2015 Synthesis and Processing Science Principal Investigators' Meeting

Hilton Washington DC North/Gaithersburg, Gaithersburg, MD November 2-4, 2015







Science

Materials Sciences and Engineering Division

<u>Top:</u> Energy dispersive x-ray analysis showing the distribution of Cu, Ag and Se elements in the synthesized CuAgSe nano platelets obtained from $Cu_{2-x}Se$ nano platelets through Ag⁺ ion exchange reaction at 300K: (a) original crystal, (b) Cu-K, (c) Se-K, (d) Ag-K. *Nanoscale* **7** (21), 9452 (2015). (Courtesy: P. Ferdinand Poudeu, University of Michigan)

<u>Right Middle:</u> Scanning transmission electron micrograph of a PNNL MBE-grown, all perovskite *pn* junction consisting of p-Sr_{0.12}La_{0.88}CrO₃ on *n*-SrTiO₃(001). *Adv. Mat.* **27**, 5191 (2015). (Courtesy: Scott Chambers, Pacific Northwest National Laboratory)

<u>Left Middle:</u> Arrays of semiconducting heterojunctions – the building blocks of ultrathin device electronics – were formed for the first time within a two-dimensional crystalline monolayer by lithographic patterning and pulsed laser deposition of sulfur. Sulfur atoms (green) replace selenium atoms (red) to convert MoSe₂ to MoS₂ in lithographically exposed regions (top) as shown by Raman spectroscopic mapping (bottom) of an actual MoSe₂/MoS₂ crystal. *Nature Commun.* **6**, 7749 (2015). (Courtesy: David Geohegan, Oak Ridge National Laboratory)

<u>Bottom:</u> From left to right, STEM image of a defect-free InGaN nanorod, and mapping images of element constituents in the InGaN nanorod. The colors of red, green, and purple represent In, N, and Ga respectively. *Nanotechnology* **25**, 225602 (2014). (Courtesy: Jung Han, Yale University)

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<i>Eugene A. Olevsky</i> , San Diego State University: Fundamentals of Spark-Plasma Sintering: Materials Processing for Energy Applications
<i>Roberto Paiella</i> , Boston University: Plasmonic Metasurfaces for the Directional Control of Light Emission and Photodetection
<i>John H. Perepezko</i> , University of Wisconsin–Madison: New Oxide Materials for an Ultra High Temperature Environment
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FOREWORD

This abstract book comprises the scientific content of the 2015 Synthesis and Processing Science Principal Investigators' Meeting sponsored by the U.S. Department of Energy, Office of Science, Office of Basic Energy Sciences, Materials Sciences and Engineering (MSE) division. The meeting, held on November 2–4, 2015, at the Washington D.C. North/Gaithersburg Hilton, Gaithersburg, Maryland, is the fifth principal investigators' meeting on this topic and is one among a series of research theme-based principal investigators' meetings being held by the MSE division.

The purpose of this principal investigators' meeting is to bring together all of the researchers funded in the Synthesis and Processing Science core research activity so they can get a firsthand look at the broad range of materials science research that is being supported in this important research area. The meeting will serve as a forum for the discussion of new results and research highlights, thus fostering a greater awareness of significant new advances in the field and the research of others in the program. The confidential and collegial meeting environment is intended to provide unique opportunities to develop new collaborations among PIs, and new ideas. In addition, the meeting affords BES program managers an opportunity to assess the state of the entire program at one time on a periodic basis, in order to chart future directions and identify new programmatic needs.

This year's meeting focuses on four topics within the Synthesis and Processing Science portfolio: non-idealities in materials, systems far from equilibrium, computational materials modeling, and hierarchical material structures. In addition, a crosscutting fifth topic is on instrumentation for better synthesis. While this is one way of organizing and presenting the research within this broad portfolio, there are many other synergies that could be highlighted and will be considered at future meetings.

Let me take this opportunity to express my thanks to all the meeting attendees, for their active participation and sharing their ideas and new research results. Special thanks are given to the Meeting Chairs, P. Ferdinand Poudeu and Scott Chambers, for their dedicated efforts and invaluable assistance towards organizing this meeting. Finally, this meeting would not be possible without the logistical support from Teresa Crockett at DOE-MSE as well as Linda Severs at Oak Ridge Institute for Science and Education (ORISE).

Bonnie Gersten Program Manager, Synthesis and Processing Science Materials Sciences and Engineering Division Office of Basic Energy Sciences Office of Science U.S. Department of Energy

Program Description

2015 DOE BES MSE Synthesis and Processing Science Principal Investigators' Meeting

The four topical sessions into which abstracts will be partitioned, and some crosscutting issues we want to explore, are:

- I. Non-idealities in materials: Can we more deeply characterize and understand the non-idealities that inevitably occur during synthetic processes for model materials? How can we effectively utilize these defects to engineer useful structures, and thereby strengthen our ability to deal with the complexities of systems operating under more realistic conditions?
- II. **Systems far from equilibrium:** Can experiment and theory be bridged to construct accurate models of the evolution of materials away from equilibrium, and thus pave the way for new states of matter?
- III. **Computational materials modeling predicting synthesis and properties:** *What new opportunities do advances in computer science and technology offer for reaching the next level of rigor in materials modeling, predicting the properties of realistic materials, and revealing new pathways for experimental materials synthesis and processing?*
- IV. **Hierarchical material structures:** *How can advanced synthetic, characterization, and modeling tools be harnessed to enable the fabrication and understanding of artificially structured materials with hierarchical arrangements of matter and the attendant novel functionalities?*

Non-idealities in materials:

Materials design and computational materials modeling often start with the assumption of ideal composition (i.e., the targeted stoichiometry with no impurities) and perfect structure (all the atoms right where we want them and their sites are well defined). Following synthetic efforts, materials characterization is carried out at some level and functional properties are measured. The results are then often interpreted in terms of the idealized model. This approach is the most straightforward and least time consuming to pursue because defects are sometimes rather hard to detect, characterize, and model. However, this zeroth-order approach can be seriously misleading because, depending on the concentrations and relative influences of the defects that are present, the resulting structurecomposition-property relationships may be at least partially, if not completely, incorrect. Some defects are the result of experimental design inadequacies and can be eliminated relatively easily. However, others are inevitable outcomes dictated by the laws of thermodynamics, particularly for more complex systems. Having the ability to detect, fundamentally understand, and predict nonidealities of all kinds would position investigators to harness these entities to advantage. As the astronomically large numbers of combinations of the more than 110 elements on the periodic chart are explored in the search for novel functionalities, having a robust strategy for detecting and dealing with non-idealities is essential.

Systems far from equilibrium:

The tendency of materials systems to move in the direction of thermodynamic equilibrium can sometimes alter system properties relative to what is sought in designing them. An example is an atomically abrupt epitaxial heterojunction between two dissimilar materials. If a heterojunction is given enough thermal energy to promote layer-by-layer epitaxial growth, entropic effects will often cause atoms at the solid/solid interfaces to diffuse across the junction, resulting in a mixed interfacial region. The properties of such a junction may or may not be what was hoped for. Accordingly, a grand challenge in materials, novel compositions, crystallographic orientations and morphologies can in principle be stabilized by synthesizing and/or processing under conditions far from equilibrium. However, there are significant gaps in our understanding of how and why systems far from equilibrium state is largely unknown. Modeling has the potential in fill in experimental knowledge gaps that defy our current suite of characterization tools. As a result, bridging theories across many length, time, and energy scales in order to elucidate organizing principles of systems away from equilibrium is a grand challenge.

Computational materials modeling - predicting synthesis and properties:

With the advent of massively parallel computers and the potential of exascale computing, materials modeling can be carried out with unprecedented levels of complexity and accuracy. Are these advances sufficient to turn computational modeling into a predictive synthesis tool? The new horizons include not only predicting the properties of complex material systems at equilibrium at levels of accuracy beyond DFT, but also understanding the dynamics of synthesis and phase transitions, both near to and far from equilibrium, and predicting those novel syntheses and processing pathways that would ultimately lead to new materials. Additionally, can one actually predict the structure of novel functional materials starting from a combination of elements in the desired chemical composition and stoichiometry or from the integration of elementary building blocks derived from simple crystal structures? What are challenges and opportunities for computational modeling from the perspective of practitioners?

Hierarchical material structures:

Learning to assemble hierarchical materials creates unique opportunities to explore the properties of matter at a fundamentally new level. Nanoscale crystallization from the vapor phase and in electrochemical cells, self-assembly of optoplasmonic molecules, focused electron beam induced deposition, and reactions within metal organic framework materials are some of the novel synthetic methods being explored to generate a variety of interesting and potentially useful materials structures that could impact several different technologies. At a fundamental level, our ability to design and control synthetic pathways determines final structural forms. Control of the synthesis process in turn depends in large part on the extent to which the hierarchical system of

interest can be characterized in real time. Likewise, the ability to rationally design useful synthetic pathways requires significant predictive power from modeling.

Informal discussions:

We will hold two informal evening discussions Monday and Tuesday before dinner with the goal of identifying grand challenges in materials modeling that might be achievable with new hardware and software resulting from the DOE Exascale Computing Initiative (http://www.exascaleinitiative.org/). The question is, what kinds of calculations would you like to see done if ~100x more computer horsepower was available for computational materials modeling? Each evening we will limit the scope of the discussion to the subject areas of the day (i.e., non-idealities in materials and systems far from equilibrium on Monday, and hierarchical material structures on Tuesday).

Our challenge this week:

This meeting brings together a diverse group of investigators with the potential to make significant progress in these four areas of importance to BES, and to stimulate the broader scientific community worldwide. Our goal for this meeting is to foster discussions and collaborations that will lead to advances in these arenas.



Synthesis and Processing Science Principal Investigators' Meeting Agenda

Monday, November 2, 2015		
7:00 – 8:00am	***Breakfast***	
8:00 – 8:15am	Introductory Remarks Meeting Chairs: Scott Chambers and Pierre Ferdinand P. Poudeu Pacific Northwest National Laboratory / University of Michigan	
Session I	Non-idealities in Materials Chair: Ivan Bozovic, Brookhaven National Laboratory	
8:15 – 8:45am	Anand Bhattacharya, Argonne National Laboratory Magnetism at Interfaces of Complex Oxides: Challenges and Opportunities	
8:45 – 9:15am	Scott Chambers , Pacific Northwest National Laboratory B-site Cation Disorder and Secondary Phase Formation in the MBE Growth of a Ferromagnetic Double Perovskite – La_2MnNiO_6	
9:15 – 9:45am	Darrell Schlom, Cornell University Point Defects—The Dirty Little Secret of Oxide Thin Films	
9:45 – 10:15am	***Break***	
10:15 – 10:45am	Maria Tamargo , City University of New York Structural Properties of Sub-monolayer Type-II Quantum Dots: Measurement and Control of Their Size and Density and Determination of Their Shape Anisotropy	
Session 2	Systems Far from Equilibrium Chair: Michael Tringides, Ames Laboratory	
10:45 – 11:15am	David Geohegan , Oak Ridge National Laboratory Nonequilibrium Synthesis and Evolution of Building Blocks in Nanostructure Growth	
11:15 – 11:45am	Yevgeny Raitses, Princeton Plasma Physics Laboratory Synergistic Roles of Plasma and Material Processes in Arc Synthesis of Nanomaterials	
11:45 – 12:45pm	***Working Lunch / Poster Introductions***	
Session 3	Division and Program Updates	
12:45 – 1:30pm	Linda Horton, Director of Materials Science & Engineering MSE Overview Arvind Kini, Team Lead, Materials Discovery, Design and Synthesis Program Updates Bonnie Gersten, Program Manager, Synthesis and Processing Science Program Updates	
1:30 – 3:00pm	Poster Session I	

Session 4	Systems Far from Equilibrium (continued) Chair: Michael Tringides, Ames Laboratory
3:00 – 3:30pm	Guangwen Zhou, SUNY– Binghamton In Situ Atomic-Scale Imaging of the Oxidation of Metals and Alloys
3:30 – 4:00pm	Amy Clarke , Los Alamos National Laboratory Multi-scale Prediction and Control of Metal Alloy Solidification Dynamics
4:00 – 4:30pm	Ralph Napolitano , Ames National Laboratory Phase Selection in Highly Undercooled Metallic Liquids: Phases, Order, and Mechanisms in Al-Sm
4:30 – 4:45pm	***Break***
4:45 – 5:15pm	Max Lagally (BESAC member), University of Wisconsin-Madison BESAC Report: "Challenges at the Frontiers of Matter and Energy: Transformative Opportunities for Discovery Science"
5:15 – 6:15pm	Discussion Leaders: James Davenport and Matthias Graf (Program Managers for Theoretical Condensed Matter Physics, MSE) Informal discussion – If the sky was the limit, what would we be modeling in the areas of non-idealities in materials and systems far from equilibrium?
6:15 – 7:15pm	*** Working Dinner / Meeting Discussions***
7:15 – 8:45pm	Poster Session I (continued)

Tuesday, November 3, 2015

	7:00 – 8:00am	***Breakfast**
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Session 5	Hierarchical Material Structures
	Chair: Jun Liu, Pacific Northwest National Laboratory

- 8:00 8:30am Xudong Wang, University of Wisconsin Development of Hierarchical 3D Nanowire Architectures by High-Temperature Derivatives of Atomic Layer Deposition
- 8:30 9:00am **Jay Switzer**, Missouri University of Science and Technology Photoelectrochemical Water Oxidation on an Electrodeposited n-Si/SiOx/Co/CoOOH Photoanode – A Close Look at the Catalyst
- 9:00 9:30am **Yves Chabal**, University of Texas, Dallas Chemistry in Confined Environments: Water Reaction in MOF-74
- 9:30 10:00am ***Break***
- 10:00 10:30am Andrei Fedorov, Georgia Tech Using Multi-Phase Energetic Jets to Achieve Understanding of Precursor-Surface Interactions and Enable New Modes of Focused Electron Beam Induced Processing (FEBIP)

10:30 – 11:00am	P. Ferdinand Poudeu , University of Michigan Electron and Phonon Transport in Nanostructured Semiconductors
11:00 – 11:30am	Bjoern Reinhard , Boston University Directed Assembly of Optoplasmonic Hybrid Materials with Tunable Photonic-Plasmonic Properties
11:30 – 12:00pm	James De Yoreo, Pacific Northwest National Laboratory Workshop report on "Crystallization by Particle Attachment" held in December 2013 in Berkeley, California, sponsored by the Council on Geosciences of the U.S. Department of Energy, Office of Science, Office of Basic Energy Sciences
12:00 – 1:00pm	***Working Lunch / Poster Introductions***
1:00 – 2:30pm	Poster Session II
Session 6	Computational Materials Modeling Chair: Mina Yoon , Oak Ridge National Laboratory
2:30 – 3:00pm	Kristen Fichthorn , Pennsylvania State University How Structure-Directing Agents Control Nanocrystal Shape: PVP-Mediated Growth of Ag Nanocubes
3:00 – 3:30pm	Boris Yakobson , Rice University Modeling 2D materials, Steps from Explaining to Predicting
3:30 – 4:00pm	Hanchen Huang, Northeastern University From Atomistic Simulations to Closed-Form Theories of Nanorod Growth, and Beyond
4:00 – 4:30pm	Timo Thonhauser , Wake Forest University Modeling Van der Waals Interactions in Metal Organic Frameworks
4:30 – 4:45pm	***Break***
4:45 – 5:15pm	Eugene Olevsky , San Diego State University Modeling of Field-Assisted Sintering: Predictive Materials Synthesis and Processing Optimization
5:15 – 6:15pm	Discussion Leaders: Peter Sushko and Kristen Fichthorn Pacific Northwest National Laboratory / Pennsylvania State University Informal Discussion – If the sky was the limit, what would we be modeling in the area of hierarchical material structures?
6:15 – 7:15pm	*** Working Dinner / Meeting Discussions***
7:15 – 8:45pm	Poster Session II (continued)

Wednesday, November 4, 2015

7:30 – 8:30am *****Breakfast*****

Session 7	Instrumentation for Better Synthesis Chair: Stacey Bent, Stanford University
8:30 – 9:00am	Nancy Dudney , Oak Ridge National Laboratory Solid Electrolytes – Probing Synthesis and Interfaces with Neutrons and Electron Microscopy
9:00 – 9:30am	John Di Tusa , Louisiana State University Techniques for Large Single-Crystal Growth of Transition Metal Compounds for Neutron Scattering
9:30 – 10:00am	John Hart, Massachusetts Institute of Technology Force-Mediated Growth of Carbon Nanotubes
10:00 – 10:30am	***Break***
10:30 – 11:30am	Summary of the State of the Art and Future Directions Scott Chambers and Pierre Ferdinand P. Poudeu Bonnie Gersten
11:30am	Meeting Adjourns

Poster Sessions

Synthesis and Processing Principal Investigators' Meeting

POSTER SESSION I Monday, November 2, 2015

- 1. Digital Synthesis: A Pathway to New Materials at Interfaces of Complex Oxides Anand Bhattacharya, Argonne National Laboratory
- 2. Using Interfaces to Create Strongly Coupled Magnetic-Ferroelectrics Darrell G. Schlom, Cornell University
- 3. Atomic-layer-by-layer Molecular Beam Epitaxy Synthesis of Cuprate Superconductors Ivan Božović, Brookhaven National Laboratory
- 4. Electronic, Magnetic, and Optical Properties of Doped Metal Oxide Epitaxial Films and Interfaces Scott A. Chambers, Pacific Northwest National Laboratory
- 5. Growth and Properties of New Epitaxial Metal/Semiconductor Nanocomposites Joshua M. O. Zide, University of Delaware
- 6. Novel Sample Structures and Probing Techniques of Exotic States in the Second Landau Level Gabor Csathy and Michael Manfra, Purdue University
- 7. Nanoscale Selective Growth and Microstructural Control of III-Nitride Growth Jung Han, Yale University
- 8. Enhanced Materials Based on Submonolayer Type-II Quantum Dots Maria C. Tamargo, The City College of New York
- 9. *Growth of InGaN Quantum Dots by Liquid Phase Epitaxy (LPE) in an MBE Reactor* Theodore D. Moustakas, Boston University
- 10. *Plasmonic Metasurfaces for the Directional Control of Light Emission and Photodetection* R. Paiella, Boston University
- 11. A Unified Understanding of Residual Stress in Thin Films: Kinetic Model and Experiments Eric Chason, Brown University
- 12. In-Situ Monitoring of Dynamic Phenomena during Solidification Amy J. Clarke, Los Alamos National Laboratory
- 13. The Dynamics of Complex Two-Phase Mixtures During Coarsening: From Dendritic to Bicontinuous Mixtures Peter W. Voorhees, Northwestern University
- 14. Ordering in Glass-Forming Liquids: A Critical Component in the Dynamical Pathway R. E. Napolitano, Ames Laboratory
- 15. *Mechanisms of Crystallization in Glass-forming Liquids: Interfaces, Diffusion, and Nucleation* R. E. Napolitano, Ames Laboratory
- 16. *Metastable Phase Competition in Highly Undercooled Metallic Liquids and Glasses* M. J. Kramer, Ames Laboratory

- 17. Growth Mechanisms and Controlled Synthesis of Nanomaterials (ERKCS81): Synthesis of Two-Dimensional Metal Chalcogenides by Laser Vaporization and CVD Kai Xiao, Oak Ridge National Laboratory
- Growth Mechanisms and Controlled Synthesis of Nanomaterials (ERKCS81): Nonequilibrium Synthesis of Ultrasmall Nanoparticles by Laser Vaporization as "Building Blocks" for Nanostructures and Thin Films David B. Geohegan, Oak Ridge National Laboratory
- Fundamental Studies of Plasma-Based Synthesis of Nanomaterials: A Joint Challenge for Plasma and Materials sciences Yevgeny Raitses, Princeton Plasma Physics Laboratory
- 20. Surface Structures Far-from-Equilibrium Michael C.Tringides, Ames Laboratory
- 21. Direct Oriented Growth of Armchair Graphene Nanoribbons on Germanium Michael S. Arnold, University of Wisconsin-Madison
- 22. Synthesis and Processing Research in Group IV Nanomembranes Max G. Lagally, University of Wisconsin-Madison
- 23. Non-equilibrium Effects in the Processing of Materials using Plasmas Lorenzo Mangolini, University of California Riverside
- 24. Understanding the Role of Viscosity and Deposition Rate during Vapor-Phase Free Radical Polymerization onto Liquid Surfaces Malancha Gupta, University of Southern California
- 25. Stability, Structure, and Molecular Orientation in Organic Glasses Produced by Physical Vapor Deposition Mark D. Ediger, University of Wisconsin-Madison
- 26. Quasiepitaxial Growth of Organic Crystalline Thin-Films Richard R. Lunt, Michigan State University
- 27. Utilizing Molecular Self-Assembly to Tailor Electrical Properties of Si Nanomembranes Pengpeng Zhang, Michigan State University
- 28. Atomic Layer Deposition (ALD) of Metal and Metal Oxide Films: A Surface Science Study Francisco Zaera, University of California
- 29. Studies of Surface Reaction and Nucleation Mechanisms in Atomic Layer Deposition Stacey F. Bent, Stanford University
- 30. Artificially Layered Superlattice of Pnictide by Design Chang-Beom Eom, University of Wisconsin-Madison
- 31. Discovery and Crystal Growth of New Oxide Phases from Metal Fluxes Theo Siegrist, Florida State University

Synthesis and Processing Science Principal Investigators' Meeting

POSTER SESSION II Tuesday, November 3, 2015

- 1. Characteristic Length Scales of Growing Nanorods An Example of Basic Science Enabled Technology Hanchen Huang, Northeastern University
- 2. Forces, Crystallization, and Assembly in Nanoparticle Suspensions Kristen A. Fichthorn, The Pennsylvania State University
- 3. Growth Mechanisms and Controlled Synthesis of Nanomaterials (ERKCS81): Modeling and Characterization of Ultrasmall Nanoparticles Mina Yoon, Oak Ridge National Laboratory
- 4. Boron-Based Nanostructures, Stability, Functionality and Synthetic Routes Boris I. Yakobson, Rice University
- 5. *Mapping the Ssynthetic Routes for 2-Dimensional Materials* Boris I. Yakobson, Rice University
- 6. Fundamentals of Spark-Plasma Sintering: Materials Processing for Energy Applications Eugene A. Olevsky, San Diego State University
- Electric-Loading Enhanced Kinetics in Oxide Ceramics: Pore Migration, Sintering and Grain Growth
 I-Wei Chen, University of Pennsylvania
- 8. Thermoelectric Properties and NMR of Complex Materials E. M. Levin, Ames Laboratory
- 9. Emergent Properties of Complex Transition Metal Compounds John F. DiTusa, Louisiana State University
- 10. *Ion Transport and Structural Evolution of Solid Electrolytes* Nancy Dudney, Oak Ridge National Laboratory
- 11. In Situ Investigations of Growth of Branched Crystal Structure Dongsheng Li, Pacific Northwest National Laboratory
- 12. In Situ Visualization and Theoretical Modeling of Early-Stage Oxidation of Metals and Alloys Guangwen Zhou, State University of New York
- 13. Mesoscale Mechanochemistry of 2D Crystal Growth A. John Hart, Massachusetts Institute of Technology
- 14. New Oxide Materials for an Ultra High Temperature Environment John H. Perepezko, University of Wisconsin-Madison
- 15. Exploring Superconductivity at the Edge of Magnetic or Structural Instabilities Ni Ni, University of California, Los Angles

- 16. *Exploratory Materials Synthesis and Characterization* Cedomir Petrovic, Brookhaven National Laboratory
- 17. Single Crystal Growth of FeAs-based Superconductors Thomas A. Lograsso, Ames Laboratory
- 18. In Situ Thermodynamics and Kinetics of Mixed-Valence Inorganic Crystal Formation Daniel P. Shoemaker, University of Illinois at Urbana-Champaign
- 19. Novel Exotic Properties of Two-Dimensional Atomic Crystals of Layered Ternary Transition Metal Chalcogenides Zhiqiang Mao, Tulane University
- 20. Laser Fabrication of Single-Crystal Architecture in Glass: Control of Morphology Himanshu Jain, Lehigh University
- 21. A Fundamental Study of Inorganic Clathrates and Other Open-Framework Materials George S. Nolas, University of South Florida
- 22. Tailoring Charge Transport and Magnetism in Complex Half-Heusler/Full-Heusler Nanocomposites Pierre Ferdinand Poudeu, University of Michigan
- 23. Thermochemistry of Oxides with Electrochemical and Energy Applications Alexandra Navrotsky, University of California, Davis
- 24. New Optoplasmonic Materials for Next Generation Energy Systems Bjoern Reinhard, Boston University
- 25. Synthesis of Three-Dimensional Nanowire Architecture with Enhanced Performance in Solar Energy Harvesting Xudong Wang, University of Wisconsin-Madison
- 26. Electrodeposition of Water-Splitting Catalysts and Epitaxial Perovskite Films for Solar Energy Conversion Jay A. Switzer, Missouri University of Science and Technology
- 27. Molecularly Organized Nanostructural Materials Jun Liu, Pacific Northwest National Laboratory
- Using Multi-Phase Energetic Precursor Jets to Enable New Modes of Focused Electron Beam Induced Processing (FEBIP)
 Andrei G. Fedorov, Georgia Tech
- 29. *Molecule–Sorbent Interactions in Metal Organic Framework Materials* Yves J. Chabal, University of Texas at Dallas

Laboratory Projects' Abstracts

1

Project Title: Digital Synthesis: A Pathway to New Materials at Interfaces of Complex Oxides Principle Investigator: Anand Bhattacharya Address: Materials Science Division, Bldg. 223, 9700 S. Cass Ave., Argonne National Laboratory, Argonne, IL 60657. email: <u>anand@anl.gov</u>

Program Scope:

In our program, we seek to create, characterize and understand superlattices and heterostructures of complex oxides with novel electronic and magnetic states. We synthesize these materials using oxide molecular beam epitaxy (MBE). This allows us to tailor chemically precise interfaces with roughness comparable to or less than the length scales for interfacial charge transfer and exchange interactions.

The complex oxides host a very diverse range of collective states of condensed matter. The richness of observed phenomena in these materials, which have also presented some of the greatest challenges to our understanding, are due to their strongly interacting degrees of freedom. Surfaces and interfaces between complex oxides provide a unique environment where these degrees of freedom may 'reconstruct' and lead to new properties that are qualitatively different from those of their bulk constituents. More specifically, we seek to discover and explore states with novel responses to external electric fields, thermal gradients and magnetic fields. We explore novel magnetic structures that arise as a result of charge transfer, electronic states that arise as a result of strong spin-orbit coupling, multiferroic heterostructures and non-collinear interfacial magnetic structures. We seek to explore materials that are known to have interesting phases where the atoms have been 're-arranged' in simple ways – for example by layering the cations in a manner such that the effects of disorder have been engineered away – to reveal new properties. We create these materials systems using ozone-assisted oxide MBE at Argonne, and characterize them using the major DOE facilities for neutron and photon scattering, and at the DOE Nanoscale Science Research Centers.

Recent Progress (since 2013):

1. Tailoring magnetic and electronic states via charge transfer at interfaces

In conventional semiconductors and metals, a mismatch between the chemical potential for charge carriers at an interface leads to charge transfer, interfacial electric fields and consequences such as band bending and Schottky barriers. In narrow band correlated insulators and metals derived from them, this charge transfer can have profound consequences. We investigated the interface between two very dissimilar perovskites, LaMnO₃ and LaNiO₃. LaMnO₃ is an antiferromagnetic orbital-ordered Mott insulator and LaNiO₃ is a paramagnetic metal. In superlattices of $(LaMnO_3)_2/(LaNiO_3)_2$, we demonstrated that charge transfer at the interface leads to a metal-insulator transition and changes in the magnetic properties as n is varied (J. Hoffman et al., Phys. Rev. B 2013). The mechanism behind the metal insulator transition, which involves a transfer of spectral weight away from the Drude peak, was further elucidated in measurements of optical conductivity of these superlattices by our collaborators (P. Di Pietro et al., Phys. Rev. Lett. 2015). Charge transfer can also have a profound influence on properties of superlattices where both constituents are *metals*, due to the relatively large Thomas superlattices screening length perovskite Fermi in the 3*d* oxides. In of $(La_{2/3}Sr_{1/3}MnO_3)_9/(LaNiO_3)_n$ where both constituent materials are metals, we used neutron scattering and x-ray absorption spectroscopy to show that interfacial charge transfer leads to a *non-collinear* magnetic structure. Our data are consistent with the development of a spin-spiral within the LaNiO_3 layers. (J. Hoffman et al., *arXiv*:1411:4344). Measurements of the angular dependence of Nernst effect combined with anisotropic magnetoresistance data confirm the non-collinear magnetic structure measured using neutron scattering on the same samples. We also have ongoing collaboration with Prof. Jian-Min Zuo's group (UIUC) and with Dr. Albina Borisevich (ORNL) to understand how charge transfer might affect local electronic properties near these interfaces using transmission electron microscopy (STEM EELS).

2. Tailoring polarity in a two-dimensional nickelate with single atomic layer control

Many of the 3*d* transition metal oxides share a common structural MO_6 building unit—a central transition metal (TM) cation octahedrally coordinated with oxygen nearest neighbors. The electronic states in these materials can be modified by tailoring the *M*-O bonds, which typically



Fig. 1: (a) LaSrNiO₄ was grown as an artificially polar material by layering the cations as $LaO^{+1} + (NiO_2)^{-1} + SrO^0$, using MBE. (b) The cation layering is verified with x-ray phase retrieval techniques. (c) The Ni-O apical bonds (upper in blue, lower in red) distort to partially screen the electrostatic dipole imposed by the polar cation ordering.

include the application of epitaxial strain in thin or pressure and isovalent films, cation substitution in bulk samples. We have found a new route to tailor the M-O bonds without changes to the strain state or stoichiometry in two-dimensional perovskite nickelate (n = 1 inthe Ruddlesden Popper (RP) series). We do this by tailoring the dipolar electrostatic interactions at the unit cell level in nominally non-polar LaSrNiO₄ via single atomic layer-by-layer synthesis using oxide-MBE. We can reconstruct the response of the crystal lattice to the induced polarity using an x-ray phase retrieval technique (COBRA). We find that the response of the O anions to the resulting local electric fields distorts the M-O bonds, being largest for the apical oxygens (Oap). It also alters the Ni valence. This structural control strategy has broad implications for tailoring electronic properties in oxides that are sensitive to the M-O_{ap} bond geometry (B. B. Nelson-Cheeseman et al., Adv. Funct. Mater. 2014).

3. Spin Seebeck Effect in Paramagnets and Antiferromagnets

We have developed a new approach for generating spin currents in *patterned* magnetic heterostructures via the Spin Seebeck effect (SSE). By using a microscale on-chip local heater, we are able to generate a large thermal gradient confined to the chip surface *without* a large increase in the total sample temperature (S. Wu et al., *Appl. Phys. Lett.* 2014; *J. Appl. Phys.* 2015). This approach allows the study of the Spin Seebeck effect at very low temperatures (even less than 1K), as the total heat load from the patterned heater wire can be readily handled by standard cryostats. Using this approach, we discovered a large spin Seebeck effect in



Fig. 2 Spin Seebeck effect measurement geometry (top panel). Spin current is detected via the inverse spin Hall effect (lower panel) for $Gd_3Ga_5O_{12}$, an insulating paramagnet. The green dotted line is the Brillouin function.

paramagnetic oxide insulators $Gd_3Ga_5O_{12}$ (GGG) and DyScO₃ (DSO), where the signal grows strongly in magnitude below ~ 20K. (S. Wu et al., *Phys. Rev. Lett.* 2015) and also in antiferromagnetic insulators (S. Wu et al., *arXiv*:1509.00439). GGG is a classical spin liquid at low temperatures (<300 mK), and we have carried out SSE experiments in this regime as well, where we now have a complete picture of how the SSE evolves in high magnetic fields ($\mu_BB >> kT$) in a paramagnetic insulator. The techniques developed here can readily be extended to other geometrically frustrated spin systems.

Future Plans:

a) *Tailoring M-O_{ap} bond lengths:* Motivated by our results in the past few years, we have plans to create and explore a number of materials systems using the synthesis approach that has been outlined earlier. In the cuprates, we will tailor the Cu-O_{apical} bond length¹ in a systematic way using dipoles and electrostatics and explore changes in properties including possible changes in T_c. In insulating single layer RP aluminates, there is a prediction² of a very large (>200%) change in the optical bandgap in polar cation ordered analogs where the Al-O_{ap} bond length, which we plan to explore.

b) Interfacial Charge Transfer in 'Mott' materials: Fermi-level mismatch and charge transfer should

occur for a broad range of oxides, beyond the nickelate/manganite interfaces that we are currently exploring. A general understanding of what happens at such interfaces is lacking because the 3d transition metal oxides have narrow bands where the charge carriers are strongly correlated and the ideas of 'band bending' have to be considered in light of the dynamic nature of the bands, i.e. the sensitivity of the band structure to filling. More specific to our recent findings, we are interested in creating nanowires of LaNiO₃ and of La_{2/3}Sr_{1/3}MnO₃/LaNiO₃ bilayers where the spin-density wave like instabilities might manifest themselves, open gaps and create spatially modulated phases.

c) Oxide MBE growth of 4d and 5d transition metal oxides: We have set up a new oxide MBE system that will enable us to synthesize thin films and heterostructures of oxides incorporating 4d and 5d transition metals. The materials of interest include perovskite iridates, that have been the focus of much recent activity due to the interplay of spin-orbit coupling and Mott physics.³ The spin Seebeck effect measurement techniques developed in our program will be extended to the 4d and 5d transition metal pyrochlores, where a number of novel ground states are found,⁴ several of which may give rise to spin currents. Metallic 4d and 5d transition metal oxides may also be effective detectors of spin currents via the inverse spin Hall effect.

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- P10. "Correlating interfacial octahedral rotations with magnetism in (LaMnO_{3+δ})_N/(SrTiO3)_N superlattices." Xiaofang Zhai, Long Cheng, Yang Liu, Christian M. Schlepütz, Shuai Dong, Hui Li, Xiaoqiang Zhang, Chu Shengqi, Zheng Lirong, Zhang Jing, Zhao Aidi, Hong Hawoong, Anand Bhattacharya, James N. Eckstein, Changgan Zeng, *Nature Communications* 5, 4283 (2014).
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Atomic-layer-by-layer molecular beam epitaxy synthesis of cuprate superconductors

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(i) Program scope

The mechanism of high-temperature superconductivity (HTS) is one of the most important problems in Condensed Matter Physics. Some basic facts - the dimensionality, the spin and the charge of free carriers, the nature of superconducting transition, the effective interaction that causes electron pairing - are still unclear. To attack these problems, we use atomic-layer-by-layer molecular beam epitaxy (ALL-MBE) to synthesize single crystal films of cuprates and other complex oxides, as well as heterostructures, multilayers and superlattices with atomically perfect interfaces, enabling novel experiments that were not possible so far.

The program impact is twofold. First, the group is the source of unique samples, including highquality HTS films and multilayer heterostructures engineered down to a single atomic layer, that are enabling breakthrough research of few dozen groups at national laboratories and leading universities in US and abroad. Second, our own in-house experiments have also brought in several important results - discoveries of HTS interface superconductivity, Giant Proximity Effect, HTS in a single CuO₂ layer, and the (de)localization of electron pairs at the superconductor-insulator quantum phase transition. [1-15] We have shown that HTS films can be quite homogeneous, having a very uniform SC gap. Charge density waves and charge glass are observed in some samples, but none for optimal doping. Phase fluctuations drive the superconducting transition at every doping, but they fade out 10-15 K above T_c , so the pseudogap must have a different origin. *In-plane* charge excitations are strongly coupled to *out-of-plane* lattice vibrations. Superfluid can be confined to a single CuO₂ layer, with T_c equal to that in bulk samples. A large enhancement of T_c is seen in certain heterostructures. Pairs exist on both sides of the superconducting transition, be it induced thermally or by doping.

These and future experiments are hoped to provide clear-cut answers to at least some of the above questions, which could significantly impact research on HTS and more broadly on strongly-correlated materials.

(ii) Recent progress

In the last two years (FY 2014 and FY 2015) we have performed over 400 ALL-MBE synthesis experiments, most of which produced atomically smooth superconducting films. Every film was characterized by RHEED, R(T) and/or χ (T) measurements and selected ones also by XRD and AFM. Many were patterned into micro- or nano-sized devices and were subject to detailed study of their physical properties and behavior. This resulted in a number of new observations, reported in 16 journal papers already published in FY 2014 and 2015, with 4 more papers completed and/or under review. The highlights are as follows.

Anomalous independence of interface superconductivity on carrier density [15]. The recent discovery of superconductivity at the interface of two non-superconducting materials has received much attention. In cuprate bilayers, T_c can be significantly enhanced compared to single-phase samples. [1] Several explanations have been proposed, invoking Sr inter-diffusion, accumulation and depletion of mobile charge carriers, elongation of the copper-to-apical-oxygen bond length, or a beneficial crosstalk between a material with a high pairing energy and another with a large phase stiffness. From each of these models, one would predict T_c to depend strongly on the carrier density in the constituent materials. We studied combinatorial libraries of La_{2-x}Sr_xCuO₄–La₂CuO₄ bilayer samples - an unprecedentedly large set of over 800 different compositions, with the doping level x spanning a wide range (0.15 < x < 0.47) and the measured Hall coefficient varying by one order of magnitude. Nevertheless, across the entire sample set, T_c stayed essentially constant at about 40
K. [15] We inferred that doping up to the optimum level does not shift the chemical potential, unlike in ordinary Fermi liquids, thus posing a new challenge to theory of HTS in cuprates.







Figure 1 | Synthesis and characterization techniques. a, The real part of mutual inductance showing diamagnetic screening (the Meissner effect) when the film becomes superconducting. The schematic of the experiment is shown in the inset. The film is placed between a drive coil and a pickup coil. The sample holder is carved out of a singlecrystal sapphire. The coils are set rigidly and the sample is spring-loaded, so that the geometry is fixed and reproducibility better than $\pm 0.1\%$. **b**, The imaginary part of mutual inductance shows that in this film, of $10x10 \text{ mm}^2$ area, T_c is homogeneous to better than 0.1 K — there are no signs whatsoever of electronic inhomogeneity or phase separation. c, The penetration depth \Box and the ac (v = 40 KHz) conductivity derived from the complex impedance. d, A schematic of sample engineered for this study at the atomic-layer level. The active (superconducting) part of the film consists of a 5 unit cells (UC) thick layer of La_{2-x}Sr_xCuO₄. (One UC, 13.2 Å thick, contains two CuO₂ planes.) It is protected by a 6 UC thick, metallic but non-superconducting La1.55Sr0.45CuO4 buffer to isolate it from the substrate, and by another 6 UC thick La_{1.55}Sr_{0.45}CuO₄ overlayer to protect it from the atmosphere. In the two layers next to the interfaces, the Sr doping level is graded and 3% of Cu is substituted by Zn to quench interface superconductivity. e, The atomic sources are aimed at the substrate at a shallow angle, which results in a gradient in the deposition rate. f, The lithographic pattern used to fabricate linear combinatorial libraries for magneto-transport measurements. The central strip, 10 mm long and 300 μ m wide, is divided into 32 segments, each 300 µm long, contacted from 64 gold pads. Longitudinal and Hall resistances can be measured at all pixels independently and simultaneously.

While cuprates superconductors exhibit many mysterious facets, but the ultimate question is why T_c is so high. The fundamental dichotomy is between the weak-pairing, Bardeen-Cooper-Schrieffer (BCS) scenario, and Bose-Einstein condensation (BEC) of strongly-bound pairs. It is hotly debated which of these pictures is appropriate for underdoped cuprates; on the other hand, it is commonly believed that on the overdoped side strongly-correlated fermion physics evolves smoothly into the conventional BCS behavior. To test this dogma, we have undertaken a comprehensive study that took ten years and encompassed several thousand of cuprate samples, probably without precedence in the history of Condensed matter physics. The large statistics enables us to identify clear trends and unravel intrinsic properties; this is essential when dealing with complex materials such as cuprates.

By atomic-layer engineering, we optimize the samples for the particular experiment. Using a continuous spread in composition we tune the doping level in steps of 0.01%. We have measured very accurately the key physical parameters (T_c , $\lambda \Box$ and ξ) of the superconducting state and established their precise dependence on doping, temperature, and external fields. We use high-throughput measurements on combinatorial libraries to study magneto-resistance and Hall effect in fields up to 90 T and measure accurately the coherence length ξ . We also measure the absolute value of penetration depth $\lambda \Box$ to the accuracy better than 1%. The synthesis and characterization techniques and typical data are illustrated in Fig. 1 below.

This wide-ranging study has been essentially completed and the results will be published soon. They bring in some great surprises, challenge the commonly held beliefs, rule out most theoretical models proposed so far, and point to an answer to our central question. In particular, the findings do not conform to BCS predictions anywhere in the phase diagram. Rather, evidence points to small, preformed pairs. This suggests that T_c is high because of strong pairing and unusual kinematics — in cuprates we may have the first example of a charged Bose gas and of *electronic* BEC. However, we emphasize that the simple BEC picture also fails at the overdoped side; unpaired fermionic charge carriers are also present, even as $T \rightarrow 0$, and their density increases with doping while the pair density decreases and eventually disappears.

(iii) Future plans

First, we plan to complete several major experiments aimed at addressing directly some of the remaining key questions about the mechanism of HTS in cuprates. These include a detailed study of scaling near the critical points, of superconducting fluctuations, interface superconductivity, proximity effects, and new phenomena in HTS nanostructures. We plan to expand the study to include few other HTS cuprate compounds.

Next, our ALL-MBE ("digital") synthesis technique enables creation of novel artificial, metastable materials. New design opportunities emerge from rich interface physics, which includes massive atomic and electron reconstructions as well as various proximity effects arising from competition between different instabilities and order parameters. This presents a new direction in search for novel superconductors, which we intend to pursue.

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(v) DOE Sponsored Publications in the Last Two Years (10.01.2011 – 10.01.2013)

1. Publications intellectually led by this FWP

1. I. Bozovic and C. Ahn, "A new frontier for superconductivity", *Nature Physics* 10, 892-895 (2014). (published December 2014)

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5. J. Wu and I. Božović, "Extremely fine tuning of doping enabled by combinatorial molecularbeam epitaxy", *APL Materials* 3, 062401 (2015).

6. V. A. Gasparov and I. Božović, "Complex conductance of ultrathin $La_{2-x}Sr_xCuO_4$ films and heterostructures", *Low-Temp. Phys.* (2015) in press.

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Electronic, Magnetic, and Optical Properties of Doped Metal Oxide Epitaxial Films and Interfaces

S.A. Chambers, S.R. Spurgeon, P.V. Sushko, Y. Du, T.C. Droubay, T.C. Kaspar - PNNL

Program Scope

We explore fundamental phenomena related to electron-hole pair creation, propagation, and lifetime, collective defect interaction, and carrier spin polarization in complex oxide epitaxial films, heterojunctions and superlattices. Understanding these phenomena paves the way for effective and scientifically informed use of oxides in photovoltaics, photo- and thermoelectrochemical, and spintronic device technologies. We aim to discover the intricate relationships that exist between composition, structure and functional properties by using molecular beam epitaxy (MBE) in conjunction with a variety of characterization methods for determining composition, global and local structure and defect densities. Electronic, optical and magnetic properties are measured and interpreted in light of realistic, as opposed to idealized, models of the material system. Deep insight is gained by coupling experiment with classical and quantum mechanical modeling efforts. A key goal is an in-depth understanding of not only how defects influence properties, but also how defects can be harnessed and controlled for useful purposes. The specific scientific themes we investigate include: (i) tailoring electronic and optical properties through alloying, superlattice formation, and strain for the purpose of efficient visible light harvesting, (ii) exploring collective defect phenomena to generate novel and useful mesoscale structures, and, (iii) using ferromagnetic complex oxides for spin injection into nonmagnetic semiconductors in simple spintronic devices.

Recent Progress

Electronic and optical properties of $Sr_xLa_{1-x}CrO_3$ based heterostructures - We have investigated the functional properties of La_{1-x}Sr_xCrO₃ ($0 \le x \le 1$) (LSCO) epitaxial films deposited by MBE using x-ray diffraction (XRD), x-ray photoemission spectroscopy (XPS), Rutherford backscattering spectrometry (RBS), x-ray absorption spectroscopy (XAS), scanning transmission electron microscopy (STEM) and related spectroscopies, electrical transport, and ab *initio* modeling. LaCrO₃ is an antiferromagnetic insulator whereas SrCrO₃ is a metal.¹⁻³ Substituting Sr^{2+} for La³⁺ in LaCrO₃ effectively dopes holes into the top of valence band, leading to $\operatorname{Cr}^{4+}(3d^2)$ local electron configurations. Core-level and valence-band features monotonically shift to lower binding energy with increasing x, indicating downward movement of the Fermi level toward the valence band maximum.⁴ The material becomes a *p*-type semiconductor at lower doping levels and an insulator-to-metal transition is observed at $x \ge 0.65$, but only when the films are deposited with in-plane compression via lattice-mismatched heteroepitaxy. Valence band XPS reveals diminution of electronic state density at the Cr $3d t_{2e}$ -derived top of the valence band while O K-edge x-XAS shows the development of a new unoccupied state above the Fermi level as holes are doped into LaCrO₃ (Fig. 1a). The evolution of these bands with Sr concentration is accurately captured using density functional theory with a Hubbard U correction of 3.0 eV (DFT + U) (Fig. 1b). Resistivity data in the semiconducting regime (x \leq 0.50) do not fit perfectly well to either a polaron hopping or band conduction model, but are best interpreted in terms of a hybrid model. The activation energies are well reproduced by DFT + U.

Significantly, LSCO remains highly transparent even as it becomes *p*-type semiconducting for $0 < x \le -0.25$ (Fig. 2a). LSCO thus constitutes a new *p*-type TCO which shows competitive performance within a structure that can readily be integrated with other oxide electronic materials.⁵ Our LSCO films all exhibit positive Seebeck coefficients (*S*), confirming *p*-type conductivity. Fig. 2b shows that *S* decreases from 321 to 80 μ V/K from x = 0.04 to 0.5, while σ increases from 1.2 to 54 S/cm. The relationship between hole concentration (*p*) and *S* is not

known for LSCO. However, p can be determined from S using a small-polaron hopping (SPH) model which is appropriate for materials with extremely low mobilities.⁶ We use the formula $S(c) = (k_B/e)\ln[2(1-c)/c]$ where k_B is Boltzmann's constant, *e* is the electronic charge, and c is the fraction of hopping sites occupied with holes. Hole creation by Sr doping at a La site thus corresponds to activation of an adjacent Cr site for hole hopping, i.e. $p(c) = cN_{Cr}$ where $N_{\rm Cr}$ is the Cr number density, 1.7 x 10^{22} cm⁻³. Based on these formulae for S(c) and p(c), we determined the hole concentration to range from 7.9 x 10^{20} to 7.5 x 10^{21} cm⁻³ with corresponding mobilities (from $\sigma = e\mu p$) of 0.009 to 0.04 cm²/Vs for x = 0.04 to 0.5. The results are shown in Fig. 2c. Although the mobility is low, the carrier concentration can easily be made high (up to nearly 10^{22} cm⁻³) by Sr substitution for La. Therefore, the conductivity can still be made high (up to \sim 50 S/cm). There are several device applications which would not be hampered by low mobility. These include rectifiers, photodetectors, solar cells and *n*-type junction field-effect transistors (n-JFET), all based on oxide pn junctions. In the n-JFET application, the high hole concentration in LSCO would cause the depletion zone to be in the *n*-type oxide with its significantly higher mobility, resulting in fast switching.

Fig. 2d shows optical transmittance for LSCO films on STO substrates in the visible and infrared regions. Transmittance was determined by averaging values at wavelengths of 420, 490, 560, 630 and 700 nm and includes the STO contribution. The spectrum for a 100 nm thick LCO film is indistinguishable from that of its substrate.



Fig. 1 (a) Valence band XPS and O K-edge XAS spectra for the $La_{1-x}Sr_xCrO_3$ film series; (b) analogous theoretical densities of states based on PBEsol + U (U = 3 eV).



Fig. 2 (a) Temperature dependence of the conductivity. The $La_{0.50}Sr_{0.50}CrO_3$ film was deposited on LAO; all others were deposited on STO. (b) Seebeck coefficients (inset shows the same measurement for an ITO film, a *n*-type TCO). (c) Room-temperature conductivity and hole concentration vs. x. (d) Optical transmission and photographs of the LSCO films deposited on STO(001).

The LSCO films are less transparent because of absorption near 450 nm, resulting in slight brown coloration. In order to compare LSCO to other *p*-TCOs, we compute a figure of merit (FOM) originally suggested by Gordon⁷ and subsequently used by Arca *et al.*⁸ This FOM is the ratio of conductivity (σ) and optical absorption coefficient (α) with reflectance (R) neglected. In the R = 0 approximation, $\alpha \approx (1/d)\ln(1/T)$ and FOM $\approx -1/(R_s \ln T)$ (in units of MQ⁻¹), where T is

the wavelength-averaged transmittance and $R_{\rm s}$ is the sheet resistance, which is in turn given by $1/\sigma d$ with d being the film thickness. Significantly, the use of R_s results in a cancellation of film thickness in the expression for FOM so that films of different thicknesses can be directly compared. A caveat is that the relatively weak dependence of transmittance on film thickness precludes quantitative comparison of films with vastly different thicknesses. We summarize the FOM values, and the data on which they are based, for our LSCO films as well as for other *p*-TCOs computed using the same formula in Fig. 3. Our highly crystalline LSCO epifilms show FOMs which are competitive with those of other *d*-orbital *p*type TCOs. We note that the directly proportional dependence of FOM on inverse sheet resistance, and the inverse logarithmic dependence of FOM on T, result in very high FOM values for highly conductive samples, even when the optical transparency is low. For example, in the limit of x = 1.0, our SCO films are metallic and the conductivity is 750 S/cm. However, T drops to 0.29, and the resulting FOM for a 50 nm film is $3050 \text{ M}\Omega^{-1}$. Similarly, the $Cu_xCr_{1-x}Mg_xO_2$ film reported in ref. 9 is doped sufficiently high that σ is 220 S/cm, but T is only 30% and F is 4600 $M\Omega^{-1}$. It is thus important to look beyond the FOM and also consider σ , T and d when evaluating *p*-type TCOs.

Finally, we show in Fig. 4 recent results for a *pn* junction consisting of MBE-grown *p*-La_{0.85}Sr_{0.15}CrO₃ on 0.05 wt. % Nb-doped SrTiO₃(001). Holes (electrons) generated by light absorption in the *p*-La_{0.9}Sr_{0.1}CrO₃ layer are expected to diffuse to the surface (bulk) based on the band alignment and built-in potentials determined by XPS and seen in



Fig. 3 Graphical representation of electrical resistance, optical transmission and figure of merit (FOM) for LSCO epitaxial films (blue squares) and other *p*-type TCOs (red squares). The numbers in parentheses marked with an F are the FOMs. The numbers in brackets are the citation numbers in ref. 5.



Fig. 4 (a) STEM-HAADF image of a p-La_{0.85}Sr_{0.15}CrO₃/n-SrTiO₃(001) heterojunction, (b) energy-level diagram extracted from XPS data, and, (c) conductive tip AFM *IV* curves measured in the dark for the heterojunction shown in (a). The sample bias was applied to the backside of the Nb-doped STO substrate.

Fig. 4b. The highly reproducible set of IV curves shown in Fig. 4c and obtained by conductive tip AFM reveals good rectifying behavior.

Future Plans

Moving forward, we are pursuing MBE-grown $p-La_{1-x}Sr_xCrO_3/n-SrTiO_3(001)$ heterojunction fabrication along with IV measurements in the dark and under illumination. We are also working on the MBE-growth and properties of $p-La_{1-x}Sr_xCrO_3/n-Si(001)$ with the goal of using the 1.1 eV band gap of Si to more effectively harvest visible light. There are formidable challenges associated with depositing epitaxial $La_{1-x}Sr_xCrO_3$ with Cr oxidized to a valence of (3) $+\delta$) directly on Si(001) without also promoting SiO₂ formation.

We are also investigated MBE-grown epitaxial films of La₂MnNiO₆ (LMNO) on SrTiO₃(001). We have found that despite the fact that Mn and Ni are present as $4+(d^3: t_{2g}^3 e_g^0)$ and $2 + (d^8 : t_{2g}^6 e_g^2)$ cations, respectively, and exhibit XMCD spectra indicating ferromagnetic coupling of Mn and Ni cations in the lattice, the volume-averaged moment per formula unit is considerably less than the expected 5 μ_B per formula unit (f.u.), even after annealing in air. The highest moment recorded thus far after annealing is ~4.5 μ_B per f.u. RBS reveals that the volume-average stoichiometry is as targeted based on atom beam fluxes to within a few percent. Additionally, STEM images show that the as-grown films are nominally very well ordered. However, STEM-EDS reveals that there is considerable chemical disorder within the B-site sublattice (i.e. there is little long-range ordering of Mn and Ni cations) for as-deposited films. Air annealing results in substantial chemical ordering of Mn and Ni, accompanied by a sizeable increase in the magnetization as the ordered double perovskite forms. Nevertheless, the moment remains below 5 μ_B per f.u. due to the formation of nanoscale NiO inclusions surrounded by Nidoped LaMnO₃. These phases were not detectable by STEM or EDS mapping. Atom probe tomography (APT) was needed to detect and characterize these inclusions. Ab initio modeling reveals that depletion of Ni from the mix of incoming atoms via formation of NiO inclusions results in Ni-doped LaMnO₃ which in equilibrium with LMNO. These results thus illustrate that unintended secondary phase formation can readily occur during the nucleation of complex oxide epitaxial films such as LMNO and that without adequate characterization, such phases can go completely undetected, yet can measurable alter functional properties.

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In-situ Monitoring of Dynamic Phenomena during Solidification

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Program Scope

Solidification of metal alloys is spatially and temporally multi-scale. We use realtime imaging to study metal alloy solidification dynamics and to inform, develop, and validate state-of-the art computational models to achieve predictive capability. At the microscopic scale, we control thermal gradient (G) and solidliquid interfacial velocity (V) during directional solidification to manipulate morphological and solutal evolution and experimentally determine the G-V combinations governing diffusion-



Figure 1. Multi-scale prediction and control of metal alloy solidification dynamics.

controlled growth transitions. We quantitatively compare our x-ray imaging of a dilute aluminum-copper alloy to three-dimensional (3D) phase-field (PF) simulations and successfully predict key microstructural characteristics, but only if solutal convection (identified by our experiments) is incorporated. At the mesoscopic scale, the evolution of dendritic arrays in aluminum-based alloys is compared to dendritic needle network (DNN) modeling. At the macroscopic scale, we use proton imaging to inform casting modeling and compare resulting structural and chemical variations with microstructural predictions. We also use dynamic transmission electron microscopy (DTEM) to study rapid solidification of nanocrystalline metal alloys films, relevant to additive manufacturing and welding. We are pursuing four-dimensional (4D) imaging (3D plus time) of hierarchical solidification structures and multi-scale experiments



Figure 2. Results from x-ray imaging of controlled growth in an Al-Cu alloy during directional solidification and quantitative 3D PF simulations, highlighting the influence of liquid convection.

to support complementary solidification and micromechanical modeling. Experimental and computational visualization of solidification, coupled with controlled processing, will accelerate the synthesis and deployment of advanced materials with designed structures, properties, and performance.

Recent Progress

Experimentally, we use real-time (electron, x-ray, or proton) imaging to spatially and temporally study multiscale solidification dynamics. We control G and V to explore microstructural selection mechanisms and identify growth regime transitions. For a dilute Al-Cu alloy, two major findings are: 1) the planar to cellular regime transition occurs at a higher velocity ($\approx 3 \mu m/s$) than predicted by diffusional growth theory ($\approx 0.5 \mu m$) [1] and 2) the dependence of microstructural length scale significantly differs from classical diffusion theory and past experiments on transparent organic analogue materials. Close to the cell to dendrite transition, primary dendritic spacing increases instead of decreases with increasing interfacial velocity. As illustrated in Figure 2, this discrepancy is a manifestation of gravity-induced convection in the liquid, which we investigated with complementary 3D PF simulations. This example highlights the importance of real-time imaging in identifying the critical physics missing from models to achieve predictive capability.

X-ray imaging of a near-eutectic Al-16at.%Cu alloy during directional solidification also revealed convection in the liquid, resulting in stray Al-rich crystals trapped within



Figure 3. X-ray images of Sn-Bi alloy growth (a) anti-parallel and (c) parallel to gravity. Red and blue correspond to Sn- and Bi-rich regions, respectively. (b,d) Locations of fragmentation events (red circles).

lamellar eutectic (Al+Al₂Cu) solid [2]. Convection is clearly observed in Figure 3, where plumes of bismuth solute appear during tin-bismuth (Sn-Bi) alloy solidification parallel to gravity. In this study, the solidification conditions were varied to examine dendrite arm fragmentation [3], which may have a significant impact on the columnar-to-equiaxed transition – a crucial event that yields a change in grain morphology and size in castings. These experimental observations unambiguously highlight the importance of gravity-induced liquid flow, despite the constrained foil configuration intended to limit convection.



Figure 4. Directional solidification of (a,b) Al-Cu and (c,d) Al-Si alloys. (Left) X-ray images and (Right) 3D DNN model predictions at the same scale, showing normalized solute concentration u.

While 3D PF is the method of choice for detailed solid-liquid interfacial modeling, larger length-scale simulations remain computationally challenging, if even feasible at all, for concentrated alloys that form complex, hierarchical dendritic networks of sharp branches during solidification. DNN modeling was developed for computationally efficient simulations of dendritic growth at the length-scale of solute transport in the liquid. The first comparisons of 3D DNN predictions with in-situ x-ray images of Al-based alloys are shown in Figure 4 [4,5]. For different metal alloys and solidification conditions, the model can predict microstructural characteristics like primary dendritic spacing critical to mechanical behavior.

Growth studies are not only limited to solidification. We

recently assessed the kinetics of liquid-liquid phase separation in an aluminum-indium (Al-In) alloy [6]. When a single liquid decomposes into two liquids with different compositions and densities (like oil and water), multiple growth mechanisms are possible, depending upon the environment and phase characteristics. Quantitative image



Figure 5. (a) An x-ray radiograph during liquid-liquid phase separation in $Al_{90}In_{10}$ and (b,c,d) diagrams highlighting growth mechanisms.



Figure 6. DTEM results of an Al-1%Si alloy showing the interface location over a few microseconds and the resulting crystallographic orientations of the grains.

analysis was used to measure In-rich liquid droplet motion and population characteristics over time. We determined that droplet growth behaviors resemble well known steady-state coarsening laws, enhanced by concurrent growth due to supersaturation. Simplistic views of droplet motion are found to be insufficient until late in the reaction, due to a hydrodynamic instability caused by the large density difference between the dispersed and matrix liquid phases.

We are studying rapid solidification of nanocrystalline Al-Si alloy films using DTEM (Figure 6), in collaboration with Lawrence Livermore National Laboratory. Interfacial velocities (m/s) have been measured and we are performing post-mortem crystallographic analysis of these rapidly solidified microstructures. This work will extend our x-ray imaging of solidification in the diffusion-controlled regime to imaging of kinetically-controlled solidification, which may provide the experimental data needed to bridge

the limiting cases. At larger length scales, we use 800 MeV protons at LANL to watch casting mold filling and solidification (Figure 7). We also perform post-mortem structural, chemical, and mechanical characterization of these castings and use in-situ and ex-situ information to inform, develop, and validate multi-scale computational models. We also use high-energy micro-focused x-rays at LANL to image larger fields-of-view and higher density alloys (Figure 8) than afforded by synchrotron x-ray imaging, with improved spatial resolution over proton imaging.



Figure 7. Proton radiography (pRad) images (top) and experimentally informed, continuum-scale simulation results (bottom) of a Sn-Bi alloy during casting mold filling.

To enable the creation of materials by design with tailored properties, we must understand the linkages between processing, structure, properties and performance. To this end,

we are exploring micromechanical testing of Al-Cu alloy dendritic microstructures made during directional solidification experiments at Argonne National Laboratory's Advanced Photon Source (APS). 3D tomography of an example micromechanical specimen, tested at LANL while



Figure 8. A highenergy micro-focus x-ray image of faceted Bi crystal growth in a Bi-Sn alloy, taken in the laboratory at LANL.

performing laboratory micro-computed tomography, is shown in Figure 9. Nano-indentations were performed on solidification microstructures to determine phase-specific mechanical properties. These early experimental results demonstrate the link from processing to mechanical behavior and are informing exploratory micromechanical modeling.

Future Plans

Several peer-reviewed journal articles are currently in preparation, including a two-part series summarizing our dilute Al-Cu alloy experimental and 3D PF modeling results, in collaboration with Prof. Alain Karma and Younggil Song at Northeastern University. Part 1 will summarize microstructural characteristics from our x-ray imaging compared to analytical expressions from solidification theory. Part 2 will present a quantitative comparison of

selected experimental results with 3D PF simulations and discuss the role of solutal convection. We are also preparing an article on x-ray imaging of recrystallization and particle-assisted abnormal grain growth in a dilute Al-Cu alloy, in collaboration with Profs. Liz Holm and Tony Rollett at Carnegie Mellon University. An article comparing proton imaging of casting mold filling with continuum-scale modeling is also in preparation, in addition to several DTEM articles.

We will continue to analyze and interpret our multi-scale imaging of solidification dynamics and make comparisons to computational modeling and perform more x-ray and DTEM experiments. In November 2015, we will image grain boundaries (GBs) during directional solidification (see Figure 10) at APS to link GB dynamics and trajectories with material anisotropy and grain orientations, in collaboration with Prof. Alain Karma. Synergistic LANL Laboratory Directed Research and Development projects are also underway, including: 1) bridging length scales (from um to m) in metal casting modeling; 2) adding convection into DNN for meso-scale simulations of realistic solidification conditions; 3) developing the hardware and software for 4D proton microscopy, which will also be applicable to 4D x-ray imaging of interest in this project; and 4) coupling of microstructural predictions from 3D DNN simulations to micromechanical modeling and comparisons with experimental results generated in this project.



Figure 9. 3D tomography of a directionally solidified Al-Cu alloy micro-tensile specimen, with and without interdendritic eutectic structure and an SEM image showing nanoindentation locations.



Figure 10. X-ray imaging of a "locked grain" below the onset of morphological instability during directional solidification of a dilute Al-Cu alloy.

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Ion Transport and Structural Evolution of Solid Electrolytes

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Program Scope

Energy storage is essential for the harnessing of renewable energies that are intermittent. Solid electrolytes are expected to play an increasing role for energy storage devices as the need for safer, mechanically robust, and energy dense chemistries grows. Stabilizing the energy dense lithium metal anode is key for low-cost advanced battery chemistries such as Li-S and Li-air. The goal of this project is to provide a detailed, fundamental understanding of the role of chemistry, crystal structure, and microstructure on the key properties of solid electrolytes under the highly non-equilibrium conditions during operation of electrochemical energy storage (EES) systems. This goal will be achieved through three synergistically arranged aims: (1) Elucidation of the effect of atomic and meso-scale structures on ion transport in solids. (2) Understanding the influence of interfaces and interphases on the ion transport and electron transfer in EES systems. (3) Revealing the structural evolution and interface contact properties of SEIs and electrode-electrolyte interfaces in solid-state electrochemical cells.

The bulk and interface properties of the solid electrolytes are determined by rigorous control synthesis conditions, but the properties may further evolve due to chemical and electrochemical reactions. Understanding these complex processes requires in situ characterization during synthesis, interface fabrication and electrochemical operation. The program encompasses new materials and compositions, as well as known model materials formed via vapor, solid, and liquid synthesis routes. This includes highly conductive oxides, phosphates, and thiophosphates.

Recent Progress

<u>Mesoscale domain structure creates ionic pathways</u>. We have demonstrated that the mesoscopic length scale, despite being largely overlooked before, could be the key in correctly interpreting ionic transport within the material. For a particular crystalline electrolyte, there is often a rather wide variation among literature reports of the bulk conductivity which is likely attributable to subtle differences in the synthesis. In our investigation, a prototype Li-ion-conducting solid electrolyte, Li_{0.33}La_{0.56}TiO₃, has been studied and the results are summarized in Figure 1. Structural analysis at the mesoscopic scale by high resolution TEM revealed the

existence of highly localized 2D Li migration pathways in a seemingly disordered phase when annealed at 1350°C, LLTO1350. Such a mesoscopic framework insinuated that the number of



Figure 1 LLTO 1350 shows unexpected higher ionic conductivity compared to that of LLTO800 (a). HR-HAADT-STEM image of LLTO1350 indicates a random distribution of Li+, La3+ and vacancies at A-sites (b). Hidden meso-scale ordering structure was revealed in LLTO

facile Li percolation pathways, in sharp contrast to previous studies, was actually maximized by quenching from a high temperature. This mechanism allowed all the grains to effectively participate in the ionic transport and thus explains the puzzling high conductivity. By pointing out the critical role of mesoscopic structures in facile ionic transport, the insights obtained here not only allows for a more comprehensive understanding of ionic conduction, but may also lead to a new paradigm for designing high-performance ionic conducting materials.

<u>Doping stabilizes the high ionic conductivity phase.</u> The synthesis mechanism of doped $Li_7La_3Zr_2O_{12}$ garnets (LLZO), one of the most promising oxide Li ion electrolytes, has been explored by in-situ neutron diffraction. It is well known that stabilizing the cubic phase and realizing the maximum ionic conductivity are sensitive to the site occupation and concentration of cation dopants. Our neutron diffraction recorded during high temperature synthesis, reveals details of the formation of the cubic and tetragonal phases. As shown in Figure 2, $La_2Zr_2O_7$ and Li_2ZrO_3 are revealed as intermediate phases in the synthesis process. The off-stoichiometry due to the evaporation of Li_2CO_3 may cause the residual of those intermediate phases in the as-



Figure 2 Fraction of the cubic and tetragonal phases of Al-doped LLZO in situ by ND during synthesis.

synthesized garnet bulk. Dopants inhibits the fast first order phase transition at \sim 630 °C, however, a small amount of tetragonal phase tends to form in the doped garnets through a diffusion process. Based on the in-situ observations, guidelines on suppressing the formation of those low-conductive phases have been provided to achieve improved electrolytic performance in garnets via the synthesis optimization.

Tuning the solid solution optimizes the ionic conductivity. A newly synthesized family of crystalline electrolytes, $Li_{3+x}Ge_xAs_{1-x}S_4$ (0<x< 0.5) has а dramatically enhanced conductivity due to the aliovalent substitution of Ge for As. As shown in Figure 3, the activation energy for the most conductive composition is only 0.17 eV, which was one of the lowest activation energies among the lithium-ion conductors. Poor chemical compatibility with metallic Li however, requires addition of a surface passivation layer. For this, 3LiBH₄•LiI deposited from solution, produced excellent lithium cycleability and a low



Figure 3 Ionic conductivity and activation energy at room temperature as a function of the Ge:As mole ratio.

interface resistance. Using the two electrolytes in tandem provides a wide electrochemical window up to 5 V versus the Li anode. Further experiments, such as those described below, are

needed to understand the gradients in electrochemical potential across the stacked electrolytes.

In situ microscopy reveals interface reaction with Li metal. Very few solid electrolytes are stable with lithium metal; doped $Li_7La_3Zr_2O_{12}$ is believed to be one which is stable, although the interface is often highly resistive. In this work, we are investigating exactly how the interface evolves when first contacted with Li. TEM methods were used to unambiguously characterize the interaction between LLZO and Li metal; the LLZO-Li contact was made in-situ within the TEM, as shown in Figure 4, thereby providing a direct comparison of the same region of solid electrolytes before and after the formation of SE/Li interfaces. In addition, the creation of artifacts associated with sample preparation and



Figure 4 The TEM set-up for *in situ* investigation of solid electrolytes-metallic lithium interfaces is schematically shown.

handling can be prevented. We observe that the interface exhibited a structure and chemistry

distinct from that of bulk LLZO. Moving forward, these observations will be correlated with the measured interfacial ionic conductivity to provide new insight regarding the microscopic origin of the LLZO/Li interfacial behavior. This is an important step in realizing durable cycling of high-capacity Li metal anodes.

<u>Artificial interface layers promote interface stability</u>. Incorporation of a thin solid electrolyte film at an electrode interface, such as for Li metal electrodes, may act as a passivation layer. But because the passivation is not understood, the synthesis of such layers is largely trial

and error. By constructing model interfaces and conducting detailed charge transfer studies, we have determined how a thin glass electrolyte film, known as Lipon, acts to passivate the interface of Li_xSi with a liquid electrolyte. Figure 5 shows that a minimum Lipon thickness of 50 nm is needed to stabilize the interface and approach 100% cycling efficiency; this critical thickness may be associated with electronic leakage current through the ultra-thin Lipon.

Further studies, where the Li counter electrode is replaced with a 3-volt cathode, are being used to probe the contact potential and potential gradient across the thin solid electrolyte.



Figure 5 Cycling efficiency for Lipon coated Si anode as a function of the Lipon thickness

Future Plans

As shown by these examples, there is still much to learn about how precise control of the synthesis refines the crystalline phase and lattice structure to promote facile ion conduction. We will continue to investigate sulfide and oxide solid electrolytes, particularly the meso-scale features which are being revealed for the first time. Studies of the interfaces formed of solid electrolytes contacting lithium and other reversible electrodes will fill a critical knowledge gap. Facile ion transport across such interfaces is critical to practical solid state devices. Future work will aim to integrate our neutron, electron microscopy and electrochemical capabilities to reveal the intrinsic interface stability, ion transport paths, and the role of reaction or barrier layers. This research tackles the grand challenges for advanced electric energy storage via the discoveries of new functional materials that enable affordable and safe storage of electricity in large scale.

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Growth Mechanisms and Controlled Synthesis of Nanomaterials (ERKCS81): Nonequilibrium Synthesis of Ultrasmall Nanoparticles by Laser Vaporization as "Building Blocks" for Nanostructures and Thin Films

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Program Scope

The overarching goal of the research program is to understand the link between the growth mechanisms and the resulting structure of nanoscale materials. The emphasis is on the development of real-time methods to induce and probe chemical and physical transformations away from thermodynamic equilibrium, in order to controllably synthesize nanomaterials with enhanced properties resulting from metastable structures. The approach relies on correlating the real-time diagnostic measurements with predictive theoretical methods and post-growth characterization by imaging, spectroscopy, and atomic-resolution analytical electron microscopy, to develop a framework for the deterministic synthesis of nanomaterials with desired properties.

Specific aims of the program are:

- (1) To reveal the kinetic pathways by which "building blocks" are involved in the growth of nanostructures through the development of real-time measurement approaches and modeling.
- (2) To understand the special role of nonequilibrium growth environments in capturing metastable phases and structures with novel nanoscale properties through the development of new synthesis and processing approaches incorporating in situ diagnostics.
- (3) To understand the atomistic interactions governing the design and synthesis of nanostructures with specific configurations and functionalities through predictive theory and associated experiments.

Recent Progress

One of the great challenges in understanding the synthesis of nanostructures is to identify the key precursors and reaction pathways leading to different hierarchical assemblies and determinable phases. We employ time-resolved in situ spectroscopic and imaging diagnostics to characterize the vapor phase growth environment well as to measure the kinetics of as nucleation. growth, nanostructure and termination. However, identifying the key precursors, and fundamental "building blocks",



Figure 1. (a) Gated images of hot Pt nanoparticles generated by pulsed fs-laser vaporization were captured by intensified CCD-array imaging to understand their propagation in vacuum (shown) and their slowing dynamics in background gases (not shown here). (b) The model developed from this study permitted the understanding of how nanoparticles generated in ns-PLD by condensation within a propagating atomic/molecular laser plume can penetrate background gases significantly beyond the normal plume range, to deposit nearly pure fluxes of ultrasmall nanoparticles for the assembly of new architectures.

that we hypothesize govern the evolution of interfaces during nanostructure nucleation and growth is typically extremely difficult.

Recently we have investigated the nonequilibrium growth conditions and tunability of the laser vaporization process to produce nearly-pure fluxes of ultrasmall nanoparticles (UNPs) with diameters ~ 3 nm. These UNPs were then deposited by pulsed laser deposition (PLD) and investigated as well-defined "building blocks" for the assembly of both two-dimensional (2D) metal chalcogenide nanosheets, and metal oxide (principally TiO₂) nanostructures. This phenomena of nanoparticle formation is regarded as a complicating factor for the formation of smooth epitaxial films in PLD, however we are exploiting the formation of UNPs as a method of stoichiometric transfer of transformable, metastable "building blocks" for synthesis of a variety of nanostructures.

As shown in Figure 1(a), to understand how nanoparticles propagate in background gases we used gated, intensified CCD-array imaging of very unique, pure nanoparticle clouds produced by femtosecond-laser through-thin-film-ablation of nm's-thin films. The narrow velocity distribution of the hot Pt nanoparticles ejected directly from the surface could be characterized by the images, and provided a unique opportunity to understand how nanoparticles propagate in background gases. In associated experiments, using a second time-delayed laser pulse and imaging the Rayleigh scattered light from the nanoparticles, the slowing and stopping of ~160 nm Pt nanoparticles in different Ar pressures was directly measured and found to occur in accordance with an Epstein drag model (e.g., stopping in 25 Torr Ar at a distance of 10 mm within 200 µs). These measurements allowed the development of model predictions for nanoparticle slowing in background gases, and along with it a new discovery for plume propagation in PLD (as illustrated in Figure 1(b)). Ultrasmall nanoparticles that form by condensation in the slowing atomic and molecular plume were predicted to propagate significant distances (e.g., 7.5 cm at 0.1 Torr), well beyond the typical plume range of atoms and molecules, thereby explaining the formation of architectures consisting of pure nanoparticles in our experiments. This ability to form plumes of pure nanoparticles permitted the exploration of UNPs as "building blocks" for nanostructure growth in our experiments.

Two-dimensional metal chalcogenides – from nanosheets to large single crystals

Recently we demonstrated the first direct PLD of functional metal chalcogenide nanosheet networks by laser vaporizing a pure GaSe crystalline target in backround Ar. Plume propagation was characterized by in situ ICCD-imaging. High (1 Torr) Ar background gas pressures were found to be crucial for the stoichiometric growth of GaSe nanosheet networks. As shown in Figure 2(a), we discovered that the "building blocks" responsible for the stoichiometric transfer of material from target to substrate amorphous were



Figure 2. (a) Ultrasmall nanoparticles of amorphous GaSe produced by laser vaporization of a GaSe target can be collected at room temperature or deposited in nanoparticle architectures. When deposited at 500-750°C, they serve as "building blocks" to grow few-layer GaSe nanosheet networks in lateral or vertical orientations, with size and orientation determined by growth conditions. (b) Patterns of these amorphous nanoparticles (GaSe or MoSe₂) can be deposited, and transferred by thermal annealing to a nearby receiver substrate for the growth of large mono- to few-layer GaSe or MoSe₂ single crystals.

GaSe UNPs. UNPs of other metal dichalcogenides, such as $MoSe_2$, provided similar results with the layer number of the nanosheets controllable by the number of laser pulses. The nanosheets were found to have excellent crystallinity, and the networks exhibited high photoresponsivity. As shown in Figure 2(b), to understand the conversion process, amorphous UNPs of both materials were deposited on quartz substrates in different patterns, then covered with a receiver substrate to form a confined vapor transport growth (VTG) reactor, and thermally annealed in background Ar gas. Large monolayer crystalline domains (~ 100 μ m lateral sizes) of GaSe and MoSe₂ were found to grow on the cooler receiver substrate, or continuous monolayer films if desired, with the coverage and layer number controllable by the "digital" nature of the PLD process. This novel PLD-VTG synthesis and processing method offers a unique approach for the controlled growth of large-area, metal chalcogenides with a desired number of layers in patterned growth locations for optoelectronics and energy related applications. Time-resolved, in situ diagnostics of the growth kinetics for both processes are in progress.

Hierarchical Assembly of Crystalline Nanostructures from UNP "Building Blocks" – Black TiO₂

Similarly, using 'amorphous' ultrasmall nanoparticle (UNP) "building blocks" deposited by PLD, the formation of metal oxide mesoscale nanoparticle architectures, nanorods, and nanosheets with interesting metastable phases has been recently discovered. As shown in Figure 3 (top panel), ~ 3 nm TiO₂ UNPs deposited by PLD in 30-100 mTorr O₂ can be accomplished at room temperature to result in nearly pure hierarchical assemblies of nanoparticle networks. These architectures can be

crystallize post-annealed to into hyperbranched, mesoporous architectures that have been used as catalyst supports and functional electrodes for dye sensitized solar cells and photocatalytic water splitting. However, the particles can also serve as 'building blocks' dynamically to incorporate/evolve into novel crystal phases and structures on heated substrates such as $TiO_2(B)$, cubic TiO_2 , or 'black TiO_2 ' depending on the kinetics and thermodynamics. A variety of nanostructures such as crystalline nanorods, crystalline 2D nanosheets, or crystalline films can be obtained. Understanding how the phases of nanoparticle assemblies evolve from UNPs deposited at different temperatures requires an understanding of phase evolution in individual nanoparticles and at nanoparticle interfaces, which we are investigating with controlled synthesis experiments, state-of-the-art electron microscopy, and modeling.

Recently, in controlled annealing of TiO_2 amorphous UNPs, we discovered a new form of "black" TiO_2 that demonstrates that the synthesis pathways have a critical influence on the formation of properties and



Figure 3. (top) Ultrasmall nanoparticles of amorphous TiO_2 produced by laser vaporization and collected at 25°C form hierarchical nanoparticle architectures. When deposited at 800°C, however, anatase nanorods are formed. (middle) Controlled experiments annealing amorphous UNPs collected at RT form larger nanoparticles of a new form of "black TiO_2 ". EELS spectra reveal the emergence of a stable Ti_2O_3 phase responsible for the black color as visualized (bottom) with ultrahigh resolution Z-STEM and associated modeling of defect evolution.

functionality. Black and other forms of reduced TiO₂ are interesting because of the band gap reduction that is associated with the color change that occurs when UNPs synthesized by pulsed laser vaporization are annealed in a highly reducing atmosphere. The dramatic bandgap reduction to ~ 1.8 eV is key to increased absorption of visible light that leads to higher efficiency of TiO₂ in various photoelectrocatalytic processes. Characterization by atomic-resolution TEM imaging in Fig. 3 shows that although the as-synthesized UNPs are clearly identifiable by their shape, Selected Area Electron Diffraction (SAED) reveals that they lack coordinated crystalline order. After annealing in Ar the films of such particles turn black and particles of varying size, crystallinity, and phase can be clearly identified. Figure 3 (middle) illustrates that amorphous UNPs sinter and evolve a structure with a quite different phase evolution than that obtained by annealing crystalline nanoparticles. Depth profiling using highly spatially-resolved Electron Energy Loss Spectroscopy (EELS), Nano Beam Electron Diffraction (NBED), and atomic resolution TEM were performed on a representative rutile particle of 15 nm size illustrates the range of possible product states of the various reaction pathways. The O-K edge EELS shows that the particles evolve from a rutile phase at their core, with the peaks broadening as the 1-2 nm surface layer is approached. The switching of the intensity ratios of the two main EELS peaks near the surface layer uniquely identifies the formation of Ti_2O_3 . As the oxygen deficiency increases during crystallization from the center of the ultrasmall particle, the phase changes from pure rutile, to defective rutile, and finally the oxygen deficiency becomes so severe that a transformation into Ti₂O₃ occurs. These measurements show that the present black TiO₂ is actually a core-shell rutile-Ti₂O₃ structure. The similarity in the EELS of very small particles and the surface layer identifies the disordered 1-2 nm near surface region as a viable model for the structure of very small particles. This is an important conclusion because it paves the way for using theory and computational modeling to treat the formation of TiO₂ UNPs from a finite number of atoms that can be correlated directly with atomic scale resolution measurements.

Future Plans

The evolution of ultrasmall nanoparticle "building blocks" into 2D layered crystals or 3D nanostructures, illustrated here through experiments, provides a unique opportunity to link atomic-resolution electron microscopic characterization with new modeling approaches to realistically describe the evolution of interfaces and phases. Through the use of monochromated EELS to characterize band structure and band gaps of individual nanoparticles to the use of nanobeam electron diffraction to investigate the origins of sub-nanometer structure within individual 'amorphous' nanoparticles, our project is advancing electron microscopy as a tool to understand nanostructure evolution in concert with new modeling approaches. Linking these descriptors within the framework of computer simulation is a goal of the project. UNPs are large, yet computationally-tractable systems. Our ambitious plans to understand their evolution through this combined microscopy/modeling approach are described in a separate abstract, where progress on the identification of structural evolution within 3D TiO₂ UNPs has already been made, and the evolution of 2D phase and structure is also described.

For the vapor transport growth of two-dimensional materials, where varieties of precursor "building blocks" have not yet been well-defined in the literature, we are studying both typical growth conditions within CVD reactors and plan to characterize the growth environment using gas-phase laser spectroscopy. Through the introduction of tunable fluxes of reactants provided by pulsed laser vaporization plumes in background gases, we plan to controllably investigate the effects of altering the flux of materials from atomic and molecular units, to cluster and particulates. In addition to the need to develop growth models that accurately describe the type and mobility of precursor species on substrates, a great variety of fundamental questions exists for the growth of 2D materials,

including the role of the substrate, the evolution of edge states, causes for compositional variations and defects. As we have done with graphene and nanotubes in the past, we are planning to "watch" 2D crystals grow using time-resolved imaging and laser spectroscopy. Microscope-based laser spectroscopy of the photoluminescence, Raman scattering, absorption, and other informative nonlinear effects have been developed and are routinely used to post-characterize 2D crystals. Our plans involve *in situ* use of these techniques during 2D crystal growth within microreactor environments to understand and control defects, doping, edge structure, and layer stacking. Progress and plans in these areas are described more fully in a separate abstract.

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FWP: Novel Materials Processing and Preparation Methodologies **Project:** Thermoelectric Properties and NMR of Complex Materials

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Project Scope

The objectives of the Novels Materials Processing and Preparation Methodologies FWP are to quantify and control processing-structure-property relationships: the science of how chemistry, structural state and phase assemblage determine the properties of highly functional materials, manipulate and design materials functionality, and test theoretical predictions about properties of materials including thermoelectric. These materials enable to convert thermal energy to electrical utilizing the Seebeck effect and attract great attention for a long time. However, there are indications that a fundamental understanding of the Seebeck effect is still lacking. Our goal is to establish correlations between the (i) Seebeck coefficient, and (ii) composition, synthesis, crystal structure, carrier concentration, effective mass and scattering, using complex tellurides as model systems. PI E.M. Levin, who conducted research in the area or thermoelectric materials during last several years, joined Novel Materials Processing and Preparation Methodologies FWP since 2014. An advantage for FWP is that he brought an expertise in the area of energy-related materials and their characterization, while an advantage to him is that expertise of FWP in synthesis of high quality materials should be used for better understanding of fundamental properties of various materials.

Recent Progress

During last two years we have studied complex tellurides and silicides by X-ray diffraction at various temperatures, microstructure using electron scanning microscopy, composition by energy dispersive spectroscopy, Seebeck coefficient, electrical resistivity, and thermal conductivity, and ¹²⁵Te and ²⁹Si nuclear magnetic resonance (NMR) measurements [1b-8b].

 Mg_2Si -based materials are well-known thermoelectric materials attracting attention for several years [1a-4a]. We studied Mg_2Si -Si alloys to understand possible combination of various properties of multiphase materials attributed to each phase [5b]. The directionally solidified alloy of $Mg_{45}Si_{55}$ shows the eutectic Mg_2Si -Si structure with Mg_2Si matrix and discontinuous Si network (Fig. 1).



Fig. 1. Backscattered electron image of solidified $Mg_{45}Si_{55}$ alloy from the transverse view near the top edge.

Fig. 2 shows ²⁹Si NMR spectra of $Mg_{45}Si_{55}$ with two peaks, at -177 ppm and -80 ppm. Based on literature data, these peaks can be attributed to Mg_2Si [5a] and Si [6a] phases, respectively. The ratio of the intensities of these peaks reflects the relative amount of Mg_2Si and Si phases. Note that Cu addition to Mg_2Si -Si does not change the solidification of the alloy [5b].



Fig. 2. ²⁹Si NMR spectra of $Mg_{45}Si_{55}$; the left peak should be attributed to the pure Si, while the right peak to Si in Mg_2Si .

²⁹Si NMR spin-lattice relaxation time, T_1 , measurements enable to derive the distribution of the carrier concentration in Mg₂Si-Si alloys. T_1 is determined by hyperfine coupling between the nuclear spin and free (mobile) charge carriers, and its value depends on the carrier concentration. Depending on the sample and heat treatment, T_1 for the Mg₂Si and Si phases shows two components, short and long, varying in a range between 12 and 300 s. Using calibration data for ²⁹Si NMR, the carrier concentration was estimated, which varies from $\sim 7 \times 10^{18}$ to $\sim 9 \times 10^{19}$ cm⁻³.

Measurements of the Seebeck coefficient, electrical resistivity, and thermal conductivity show that electronic transport in Mg_2Si -Si alloys is mostly determined by the Si phase, while the thermal transport is limited by the Mg_2Si phase. By utilizing all characterization tools, we show that various experimental methods can be used as complementary methods to better understand the individual and combined properties of multiphase alloys [5b].

Interesting results were obtained for complex GeTe-based materials. GeTe alloyed with Ag and Sb form $Ag_xSb_xGe_{50-2x}Te_{50}$ alloys, well-known high-efficiency TAGS. We studied the effects of separate replacement of Ge in GeTe by Ag or Sb ($Ag_xGe_{50-x}Te_{50}$ and $Sb_xGe_{50-x}Te_{50}$ alloys) [7b]. Our data (Fig. 3, at the top) show that Ag reduces the Seebeck coefficient, while Sb increases it. Within common model for metals and semiconductors [7a], $S \sim m^*/n^{2/3}$, where m^* is carrier effective mass and n is the carrier concentration; if m^* is constant, S mostly depends on the carrier concentration. The carrier concentration in tellurides can be obtained from ¹²⁵Te NMR spin-lattice relaxation measurements [2b].

¹²⁵Te NMR spectra for GeTe-based alloys are shown on Fig. 3 (at the right). The NMR signal for GeTe is observed at +160 ppm. Replacement of Ge by Ag shifts the signal to more positive values. In contrast, replacement of Ge by Sb shifts the signal to more negative values. Such changes can be attributed to the changes in the Knight shift, which depends on T_1 and, therefore, on the carrier concentration. ¹²⁵Te NMR spin-lattice relaxation measurements confirm that Ag reduces T_1 , while Sb increases it, i.e. Ag increases the carrier concentration while Sb reduces it.

Comparison of the data for GeTe, $Ag_xGe_{50-x}Te_{50}$, $Sb_xGe_{50-x}Te_{50}$, and $Ag_2Sb_2Ge_{46}Te_{50}$ allow us to confirm theoretical prediction [8a] that Ag and Sb in GeTe ($Ag_xGe_xGe_{50-2x}Te_{50}$ materials or TAGS) *form atomic pairs*. The existence of such pairs can explain high efficiency of TAGS materials.





Fig. 3. Temperature dependencies of the Seebeck coefficient (at the top) and ¹²⁵Te NMR spectra (at the right) of GeTe, $Ag_xGe_{50-x}Te_{50}$, and $Sb_xGe_{50-x}Te_{50}$. ¹²⁵Te NMR spectra for $Ag_2Sb_2Ge_{46}Te_{50}$ are shown for comparison.

Earlier we found that doping of TAGS-85 (Ag_{6.5}Sb_{6.5}Ge₃₇Te₅₀) with 1 at.% rare earth Dy significantly enhances the Seebeck coefficient and thermoelectric efficiency [9a]. To better understand the effects of rare earths on crystal structure and thermoelectric properties of GeTe-based materials, we have synthesized and studied Ge₄₉Te₅₀R₁ alloys with R = La, Pr, Gd, Dy, and Yb, i.e. rare earth elements with different atomic size and localized magnetic moment [8b]. We found that rare earth atoms can produce strong effect on some parameters. GeTe has low-temperature rhombohedral and high-temperature cubic structure, and rhombohedral-to-cubic transformation may affect its thermoelectric properties. The transition can be seen via evaluation of two Bragg peaks, (024) and (220) (Fig. 4). The temperature when GeTe becomes mostly cubic, T_{cubic} , is ~660 K, while replacement of Ge by 1 at.% La increases T_{cubic} up to ~700 K.



Fig. 4. XRD patterns showing (024) and (220) peaks for (a) GeTe and (b) $Ge_{49}Te_{50}La_1$; replacement of Ge by 1 at.% La increases the temperature of rhombohedral-to-cubic transition.

We also have found that alloying of GeTe with Gd and Dy (atoms with large magnetic moments) results in significant magnetic contribution to the Seebeck coefficient. In general, a comprehensive study of GeTe-based materials allowed us to establish important correlations and significantly increase our understanding of thermoelectric materials.

Future Plans

♦ Synthesize several series of GeTe-based materials where Ge is replaced by various elements and conduct a comprehensive study using common and advanced (¹²⁵Te NMR) methods.

• Establish structure–property correlations for complex GeTe-based materials, to understand a role of rhombohedral-to-cubic transformation on the Seebeck coefficient and other related properties.

• Test our hypothesis: (i) [Ag+Sb] in $Ag_xSb_xGe_{50-2x}Te_{50}$ (TAGS materials) form atomic pairs, (ii) atomic pairs affect the carrier effective mass and density of electron states near the Fermi level, (iii) these pairs result in high efficiency of TAGS materials.

◆¹²⁵Te NMR in complex tellurides still needs to be better understood. The emphasis is to continue to develop algorithms for use of NMR spectroscopy to obtain useful information from spin-lattice relaxation measurements, signal width, Knight and chemical shifts for complex tellurides.

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In situ investigations of growth of branched crystal structure

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Program Scope

The objective of this project is to develop an understanding of the formation mechanisms that determine nanocrystal size and morphology to enable the design of highly branched nanowires with tailored physical and chemical properties. Here I will develop a predictive understanding for two important categories of non-classical processes of branched nanowire formation: (1) particlebased growth (i.e. TiO_2 branched nanowire growth[1], Figure 1A, particularly oriented attachment (OA), and (2) competition between classical and non-classical



Figure 1. SEM images of branched TiO_2 nanostructures¹; B: PbS "pine-tree" nanowires²;

mechanisms, specifically screw dislocation-driven trunk growth and vapor-liquid-solid (DD-VLS) branch nucleation (i.e. PbS branched nanowire growth[2], Figure 1B).

Development of a predictive understanding of those processes requires data on the dynamics of nanocrystal formation as it happens — rather than just information about the nanocrystals after they are formed. This work will employ *in situ* transmission electron microscopy and atomic force microscopy, which provide direct observation of atomic structure under actual conditions of the synthesis process, to investigate the movement and assembly of the precursors that are key elements in the synthesis of nanowires. This phenomenon will be correlated with the surface charge of the precursors, as well as the orientation-dependent forces between them. Finally, the role of competition between classical and non-classical mechanisms will be determined.

Recent Progress

Our previous *in situ* TEM investigation in iron oxide system shows that, in the iron oxide system, primary particles interact with one another through translational and rotational diffusion until a near-perfect lattice match is obtained either with true crystallographic alignment or across a twin plane[3]. Oriented attachment then occurs through a sudden jump-to-contact. Analysis of the acceleration during attachment indicates it is driven by electrostatic attraction. Ex-situ TEM analysis shows that the TiO_2 nanowire branching occurs through attachment of anatase nanoparticles to rutile wires on a specific crystallographic plane for which the anatase-to-rutile transformation leads to creation of a (101) twin plane.

Our hypothesis is that attachment is due to reduction of surface energy and the driving forces that bring the particles together are a mix dipole-dipole interactions, van der Waals forces, and Coulombic interactions. Therefore they can be controlled via pH, ionic strength (IS), and ionic speciation.

In our preliminary investigation, we first study particle mediated growth system. We will employ the AFM-based DFS approach to directly measure the forces, which drives OA events, between crystal facets to determine the absolute free energy of binding directly comparable to in situ TEM result. We investigate the orientation-dependent forces between nanoparticles.

In my preliminary experiments, I have successfully fabricated crystallographically oriented face-specific AFM "tips" (Figure 2A and B) and measured forces between (001) planes of ZnO, TiO₂, and mica. Initial DFS measurements of the forces between (001) crystal basal planes of mica, (001) planes of and (001) planes of ZnO show that the forces have strong relationship to pH, IS, and crystal orientation as shown in Figure 3A and B.



Figure 2. Customized crystallographic TiO_2 crystal (101) and mica (001) as AFM tips



Figure 3. DFS measurements of the forces between (001) crystal basal planes of ZnO, (001) planes of s of mica, showing strong relationship between forces and pH and IS of solutions.

Future Plans

Our future plan involves (1) investigation of TiO2 branched nanostructures formation via OA and extraction of the kinetic parameters that control them via in situ TEM, DFS/AFM and

zeta potential; (2) investigation of PbS pine tree formation via DD-VLS and the thermodynamic and kinetic factors via in situ TEM; (3) study of electron beam effects study carried out throughout the in situ TEM experiments

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Publications

N/A (Project just started Aug, 2015)
Molecularly Organized Nanostructural Materials

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Program Scope

The goal of this project is to develop innovative approaches employing molecularly directed interfacial reactions to control crystallization and self-assembly of functional nanocomposites for energy storage and other applications. The central challenge is to develop principles to predict the synthesis of hierarchical materials with structural ordering across scales from atomic to nanoscale and beyond. This project will focus on interfacially controlled nucleation in synthesizing carbon-metal-metal oxide nanocomposite materials. The knowledge gained will be extended to understand and control self-assembly of materials with both atomic and longer length-scale ordering, and furthermore, to develop principles for synthesizing hierarchical structures through multi-generation nucleation processes. State-of-the-art transmission electron microscopy (TEM), atomic force microscopy (AFM), nuclear magnetic resonance (NMR), and extensive molecular and mesoscale computer modeling will be used to elucidate fundamental mechanisms of interfacial binding, nucleation and self-assembly.

Recent Progress

Graphene templated synthesis approaches for nanosized energy storage materials: We have demonstrated that specific carbon surfaces can function as molecular template to control nucleation using functionalized graphene sheets as model materials. One example is Chevrel phase MxMo6T8 (M=metal, T=S, Se, or Te) for reversible multivalent ions intercalation with and without the presence of nucleation directing substrates (Chem Mat, 2014). Graphene sheets direct the nucleation and growth of particles and were critical for obtaining nanoscale particles. The synthesized nanocubes were tested as the active materials for multivalent Mg ions and Zn ions storage and were found to have substantially improved intercalation kinetics and higher reversible capacity. Graphene template synthesis was also used for preparing SnSb anode materials for Mg ion batteries (Adv. Mat., 2015). The SnSb alloy particles were synthesized on graphene substrate using SnCl₂ and SbCl₃ as precursors and a combination of solvothermal reaction and hydrogen reduction processes. We revealed that the pristine alloy SnSb particles experienced particle breakdown and phase segregation to Sn-rich and Sb-rich phases upon insertion of Mg ions. Both experimental analysis and density functional theory simulations suggest that the Sn-rich phase is particularly active and provides most of the capacity whereas

the Sb-rich phase is not as active. The interface between these two Sb-rich and Sn-rich phases is found to play a key role in promoting the formation and stabilization of the cubic Sn phase that is favorable for fast and reversible Mg insertion.

Figure 1. STEM characterization of Mo₆S₈ and the reaction mechanism. Magnesiated A-E) and demagnesiated F-I) electrodes. (A,F) Overview of the particle prior. (B,G) Simultaneous HAADF detector intensity map and EDS elemental intensity maps for Mg (C,H), Sn (D,I, yellow), and Sb (E,I, red). The EDS maps for Sn and Sb have been overlaid in (I) to highlight the correspondence between the phase segregated domains with regions of high or low Mg content in(H). The Mg elemental maps are displayed in cyan-hot, whereblack/dark blue is low Mg intensity and light blue/white is high Mg intensity. J. Schematic illustration of the electrochemical reaction mechanism of SnSb particles with Mg Pristine SnSb particle ions. experiences phase segregation breakdown and during electrochemical activation, and reversible Mg ion storage for activated SnSb alloys.



The role of high surface carbon was further studied in carbon-V₂O₅ composites for energy storage and the materials transformation mechanism during charge-discharge (to be submitted). The high surface area carbon was synthesized using resorcinol and formaldehyde as precursors (RFC), and the composite material was synthesized using the ambient hydrolysis deposition method with controlled loading and calcination of vanadium oxytriisopropoxide to V₂O₅. We found that the crystalline phase transition of V₂O₅ was substantially hindered by the interfacial interactions between carbon surface and V₂O₅ clusters, which helps retaining the high surface area of the composite at ~ 600 m²/g and the highly dispersed state of the V₂O₅. We found that the crystalle with highly dispersed V₂O₅ showed high capacity exceeds 300 mAh/g and fast charge transfer kinetics, and has potential as the cathode for Mg batteries. We identified that the Mg ions storage mechanism is through molecular reactions with the highly dispersed V₂O₅ and is surface controlled, and shows pseudocapacitive behavior.

Carbon Surface for Manipulating Electrochemical Reactions: In addition to controlling nucleation, carbon surfaces can modulate electrochemical reactions (Nature Comm, 2014). This concept is demonstrated in Li-S batteries. Lithium-sulfur batteries have high theoretical energy density and potentially low cost, but significant challenges such as severe capacity degradation prevent its widespread adoption. We conducted a fundamentally new design using electrically connected graphite and lithium metal as a hybrid anode to control undesirable surface reactions on lithium. The lithiated graphite placed in front of the lithium metal functions as an artificial self-regulated solid electrolyte interface layer to actively control the electrochemical reactions

and minimize the deleterious side reactions, which significantly improves performance. Li-S battery incorporating this hybrid anode delivers a capacity of more than 800 mAh g-1 for 400 cycles at a high rate of 1737 mA g-1, corresponding to only 11% capacity fade and a Coulombic

efficiency above 99%. This simple hybrid concept may also provide new lessons for protecting metal anodes in other energy storage devices.

Figure 2. Schematic of the hybrid anode design to manipulate the surface reactions on Li-S batteries. In the intrinsic cell design, the anode is made of Li metal connected with graphite. Lithiated graphite in the integrated anode multifunctions as an artificial, self-regulating SEI film on Li surface to dynamically "pump" Li+ ions. In addition the lithiated graphite works as a physical barrier to modulate the polysulfides concentration gradient in the cell, transferring the sulfur "contamination" issue from Li metal to the graphite side.



Fundamental study of nucleation: Hierarchical

porous materials with crystalline structure are one of the most important families of complex functional material. The molecular assembly mechanism of the framework in these materials on which the structure and morphology control is based remains largely unknown. In-situ atomic force microscopy (AFM) provides the one of most direct way to answer these mechanism questions by observing nucleation and growth of metal organic frameworks (MOFs) in real time. Herein we study the nucleation and growth process of a MOF, zeolitic imidazolate framework ZIF-8 by using ZnO (001) face as the substrate and 2-methyl-imidazole as the linker. The nucleation of ZIF-8 occurs through the dissolution of ZnO and complex of released Zn2+ with the linker. The slow rate of ZnO dissolution together with continuous flux of linker solution makes possible to control the driving force for ZIF nucleation. The nucleation process at different concentrations of linker is studied, at the lowest concentration of 5 mM, no nucleation of ZIF is observed at 60 °C, at highest concentration of 500 mM, the nucleation of ZIF too fast to be monitor in AFM time scale (~3 min). At the concentration of 25 mM, 50 mM and 75 mM at 60 °C, the detailed nucleation and growth process of ZIF-8 is studied. The nucleation is highly selective on different sites. That is, the nucleation of crystallites has preference on the preformed step edges rather than terraces on ZnO (001) faces. The smallest observed nuclei have size up to 12.5 nm, these nuclei will merge together to form larger crystal with size of 41.0 nm and the growth rate of 1.20 nm/min. The secondary nucleation happens both at the surface and edge of ZIF-8 crystal after 34 min, the secondary nucleation at edge are more preferential than that on the surface. Our study enables direct identification of the fundamental units during the nucleation and growth stage of ZIF-8 on different crystal faces. These findings will be applicable to numerous nanoporous materials and support efforts to synthesize and design new frameworks with controlled properties. This study opens the door for quantitatively describing the fundamental nucleation phenomena is complex energy materials.

Figure 3. The in-situ AFM images of nucleation and growth process of ZIF-8 on ZnO (001) face. A) dissolution of ZnO (001) face in water. B) ZnO (001) face in the condition of 5 mM 2-methyl-imidazole and 60°C; C) ZnO (001) face in the condition of 500 mM 2-methyl-imidazole and 60°C; D) ZnO (001) face in the condition of 25 mM 2-methyl-imidazole and 60°C; he newly formed ZIF-8 nuclei merge into a larger crystal; E) the secondary nucleation of ZIF-8 on the edge and surface of ZIF-8. Scale bars: A) 1 μ m; B) and C) 400 nm; D) and E) 2 μ m.

Future Plans



1. Fundamental understanding of nucleation on well-defined nanostructured carbon substrates. This task will focus on nucleation in a range of energy relevant materials, revealing the nature of the nucleation sites, elucidating early stages of nucleation including the molecular events and phase evolution leading to the final stable structure. The materials systems will consist of metals (Pt, Au, Ni, Cu) and metal oxides (NiO, CuO, MnOx, VOx) nucleated on well-defined carbon structures including carbon nanotubes, graphene, or carbon fibers, as well as well-defined, oriented metal oxides such as ZnO and TiO2.

2. Interface controlled template-directed self-assembly and nanocrystal nucleation. This task will explore the interdependent processes of surfactant self-assembly and nanoparticle nucleation at interfaces to form ordered structures with both atomic and mesoscale ordering. Specifically, we will investigate self-assembly of anionic and cationic surfactants and block copolymers coupled with nucleation of metal oxides (SiO2, TiO2, ZrO2) on graphene and carbon nanotube substrates.

3. Higher order structures. This task will explore and apply principles of interfacially controlled nucleation to create complex higher order structures through multiple generations of nucleation events using ZnO as the canonical materials system.

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FWP: Novel Materials Processing and Preparation Methodology Project: Single Crystal Growth of FeAs-based Superconductors

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Program Scope

The *Novel Materials Preparation and Processing Methodologies* (Novel Materials) FWP is a synthesis-oriented research effort engaged in maintaining and enhancing the synthesis capabilities of the laboratory. We develop advanced processing techniques for the reproducible growth of high quality novel materials in polycrystalline and single crystalline forms. We perform detailed investigations on materials systems whose functionality is highly sensitive to synthesis pathways (e.g., thermoelectrics) to provide scientific understanding of the synthesis-structure-property relationship in newly discovered materials and in materials systems that are

difficult to process due to reactivity, volatility, and toxicity (Fe-As superconductors).

The objectives of the Novel Materials FWP are to:

- Develop unique capabilities and processing knowledge in the bulk preparation, purification, and fabrication of inorganic metals, alloys, and compounds;
- Advance our Nation's ability to synthesize and characterize high purity, high quality materials, primarily in single crystal form, but also as metastable forms, such as ribbons, powders, or films;
- Quantify and control processing-structure-property relationships: the science of how chemistry, structural state, and phase assemblage determine the properties of highly functional materials;
- Manipulate and design functionality, and test theoretical predictions about new materials.

In pursuing the objectives of Novel Materials, the FWP focuses its efforts on energy-relevant materials where reproducible synthesis is challenging and the materials properties are particularly sensitive to synthesis pathways.

Recent Progress

 $K_xFe_{2-y}Se_2$ superconductors are characteristic of phase separation feature. However, the nature of phase separation is not well understood. We have demonstrated that the superconducting phase is



Figure 1. (a) and (b) Reconstructed 3D morphology of the stripe phase in the pseudo-singlecrystal $K_xFe_{2-y}Se_2$. (c) A raw image of (0 1 0) plane used for 3D reconstruction of the volume shown in (b).

the remnant of high temperature phase after iron vacancy order-disorder transition. The

superconducting phase should not form without iron vacancy order-disorder transition. By focused ion beam-scanning electron microscopy (FIB-SEM), we further revealed that the superconducting phase forms a contiguous 3D architecture composed of parallelepipeds that have a coherent orientation relationship with the majority phase. Our results provide a reasonable explanation for the highly divergent results in the previous report on the processing techniques and stoichiometry in the starting materials [1-2].

Less work has been done in overdoped $Ba_{1-x}K_xFe_2As_2$ single crystals because it is difficult to grow high-quality single crystals with sharp superconducting transitions. We have developed an inverted temperature gradient method to grow large and high-quality BaK122 single crystals [3]. see Figure 2. The top zone is set as the cold zone, such that nucleation initiates at the liquid surface layer upon cooling. Furthermore, the surface layer saturates because of the loss of K and As by evaporation, which produces "evaporation growth" on top of the melt. Because BaK122 single crystals start to crystallize from the liquid melt surface, the likelihood of trapped flux or impurities is reduced compared to growth inside the bulk of the liquid. We harvested large crystals with in-plane size up to $18 \times 10 \text{ mm}^2$.

We have grown single crystals of bcc Fe-Ga-Zn for the first time, with up to 4.6 at. % Zn, using a 15 Bar Bridgman furnace to overcome the high vapor pressure of Zn and obtain homogeneous crystals [4]. The magnetostriction and elastic constants were measured and found to increase only slightly over those of the binary alloys, significantly short of the theoretically predicted value for a composition of Fe_{87.5}Ga_{6.25}Zn_{6.25}. Comparing the $-b_1$ values for Fe-Ga (see Figure 3), the Fe-Ga-Zn data are only 2% higher at the lowest e/a value and increase to 6% higher at the highest e/a value. Our work has definitively shown that while trends in magnetoelasticity can be predicted, the magnitude of enhancement is not accurately calculated and this discrepancy between theoretical and experimental findings





is believed to stem from the inability to simulate the random distribution of Zn and Ga throughout the bcc iron lattice.

Future Plans

LnOFeAs and AeFFeAs systems have identical crystal structures. However, AeFFeAs compounds have two building blocks, i.e., AeF and FeAs layers, instead of the LnO layers in

LnOFeAs compounds. $CaFeAsF_{1-x}$ crystals with maximum dimensions of approximately $2 \times 0.5 \times 0.0045$ mm³ were obtained from mixtures of Fe powder with CaAs and FeF₂ in the stoichiometric ratio [9]. However, superconductivity was not observed in the crystals. We propose that alternate flux materials could be Ca, Ba, CaAs, BaAs, BaF₂, CaF₂ and FeF₂.

We propose that some layered perovskite-related titanates, niobates and tantalates can act as potential substrates for thin film growth of iron pnictide and high T_c cuprate superconductors [10]. We will focus on $A_nB_nO_{3n+2}$, $A'A_{k-1}B_kO_{3k+1}$, and hexagonal $A_mB_{m-1}O_{3m}$, where A represents alkaline earth metals or rare earth metals, and B represents transition metals. Due to the very close structural relationship with cubic perovskite ABO₃, single crystals of these materials may even replace SrTiO₃, LaAlO₃, and MgO, commonly used as substrates for growth of those novel materials. We will use optical floating zone furnace techniques to grow single crystals.

We will synthesize several series of GeTe- and PbTe-based materials where Ge or Pb, respectively, is replaced by Ag, Sb, Bi, Sn, and other elements, and conduct a comprehensive study using common methods, XRD (300-800 K), SEM and EDS (both at 300 K), the Seebeck coefficient, electrical resistivity, thermal conductivity (300-800 K), Hall effect (1.8-380 K) and ¹²⁵Te NMR (250-380 K). While common methods appear to be well established, understanding the physics of thermoelectric materials with these methods always requires state-of-the-art analysis. For example, SEM imaging might be perceived as "run-of-the-mill" work, but correct interpretation of SEM results demands careful signal differentiation by varying the incident beam energy and using the advanced capabilities of a high performance instrument. Furthermore, ¹²⁵Te NMR in complex tellurides still needs to be better understood. The emphasis is to continue to develop algorithms for use of NMR spectroscopy to obtain useful information from spin-lattice relaxation time, signal width, Knight and chemical shifts, and chemical shift anisotropy for complex tellurides and other materials.

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Ordering in glass-forming liquids: A critical component in the dynamical pathway

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Program Scope

The unique feature surrounding transformation kinetics in glass-forming systems is the development of non-crystalline forms of short-range order (SRO) and medium-range order (MRO), and these can play a substantial role in the determining the transformation pathways. In this task area, we aim to understand the development of such order along with the fundamental connections to the thermodynamic forces and mechanisms that ultimately dictate the dynamical pathways involving crystallization and/or glass formation. Experiments (1, 2) and computer simulations (3, 4) have revealed SRO and MRO in glass-forming alloys, and we explore these effects in the selected model systems of Cu-Zr and Al-Sm. Fig. 1 shows a molecular dynamics prediction of the influence of cooling rate on the extent and character of regions of icosahedral order in a $Cu_{64.5}$ -Zr_{35.5} alloy, as revealed by a cluster alignment analysis method (5-7). The principal objective is to build comprehensive self-consistent descriptions of the relevant forms of ordering, the critical connections to measurable thermo-kinetic properties, and the dependence on composition, temperature, and thermal history. Here, we summarize recent progress, challenges, and future directions.

Recent Progress

Recent advancements in this task area include both computational and experimental efforts to characterize short- and medium-range order (MRO) as a function of temperature and cooling rate. The challenge here is that cooling rates accessible by molecular dynamics are several orders of magnitude greater than those attainable in experiments (Fig. 1), and we are working to close this gap from both ends. Experimentally, we are employing container-less levitation processing, laser processing, and sputtering deposition access higher (but controllable) cooling rates experimentally. Computationally, we have extended the range of our molecular dynamics simulations to mimic cooling rates several orders of magnitude lower than previously possible, yielding structures that more closely resemble experimentally obtained systems. Using the cluster alignment analysis we reported previously(8), we have examined the cooling rate dependence of medium-range order in this regime for Cu_{64.5}Zr_{35.5}, and we have quantified the aggregate character of this order in comparison with experiment. For this same alloy, we have clearly correlated dynamic heterogeneity to the structural heterogeneity by examining atomic diffusion paths relative to regions of short- and medium-range order. In addition, we have made

experimental measurements of heat capacity for undercooled liquids of $Cu_{64.5}Zr_{35.5}$, $Cu_{50}Zr_{50}$, $Al_{90}Sm_{10}$, $Al_{90}Tb_{10}$, and $Al_{80}Sm_{20}$. These efforts are described briefly below.

An accurate description of atomic structures in undercooled liquids and glasses is vital to study the phase competition and selection using molecular dynamics (MD) simulations. Conventional MD simulations utilize ultrahigh cooling rates of 10^9-10^{13} K/s. As a result, the



Figure 1 (a) The potential energy of the models as a function of cooling rate, by applying the $sub-T_g$ annealing the cooling rate can be effectively reduced to 2.8×10^7 K/s. The BMRO in the models prepared using the cooling rate of 1.0×10^{10} (b) and 2.8×10^7 K/s (c), respectively. Red and blue atoms are centers and coordinated atoms of BMRO, respectively. A typical diffusion trajectory during the $sub-T_g$ annealing approach is shown in (d) and (e), respectively. In (d), the gray isosurface is the ISRO network, the diffusing atom is shown in red when it is outside ISRO. In (e), the gray isosurface is the BMRO network, the diffusing atom is shown in green when it is outside BMRO.



Fig. 2. Comparison of MD structures with experimental measurements (cooling rate $\sim 10^6$ K/s), showing advantage of sub-T_g annealing.

obtained atomic structures can differ substantially from the real structures. We have carried out the $sub-T_g$ annealing approach to reduce the cooling rates, where the model was isothermally annealed close to the glass transition temperature for several microseconds in MD simulations. For Cu_{64.5}Zr_{35.5} metallic glasses, a cooling rate of 2.8×107 K/s can be reached after sub- T_g annealing at 700 K for 2.2 μ s, which is by far the lowest cooling rate achieved for this alloy using MD simulations. As a comparison it will take 30 times longer for

conventional MD simulations to reach the same cooling rate. The icosahedral short-range order (ISRO) and the Bergman-type medium-range order (BMRO) are significantly enhanced in the slowly cooled model. The enhanced ordering is found to have substantial impact on the dynamics most of the atomic jumps performed by the diffusing atoms are outside ISRO and BMRO. It indicates that the structural heterogeneity is closely related with dynamical heterogeneity. ISRO and BMRO form the solidlike backbone, whereas diffusion is confined to the liquid-like regions where such ordering is depleted in Cu-Zr metallic glasses.

Direct experimental measurements that correlate with the extent and nature of structural order in the system are critical to building a self-consistent comprehensive description of the thermo-kinetic landscape upon which to base prediction of transformation dynamics. One such connection lies in the structure factor, measurable by X-ray diffraction, as we have discussed (Fig. 2). Another quantity that can be used for direct comparison is the heat capacity, which reflects the structural state. However, his quantity is difficult to measure in undercooled liquids because of their unstable and transient nature. To address this issue, we have developed an integral heat (Q) method for differential scanning calorimetry (DSC) {Wang, 2014 #637}, where we use the time-dependent nature of the crystallization transition to yield various transition temperatures by varying the heating (or cooling) rate within a range that does not result in a change in the reaction products. By measuring the total integrated heat of transition, we have measured enthalpy with temperature, relative to the product crystalline phase for $Cu_{50}Zr_{50}$ and $Cu_{64.5}Zr_{35.5}$.

Future Plans

A key focus of our future work is to develop suitable order parameters that effectively describe *the evolution of SRO and MRO under different undercooling rates. Such order parameters can be* directly used in advanced sampling techniques to further accelerate the kinetics in MD simulations, such as template-assistant MD (TAMD) and metadynamics. In the TAMD approach, extra forces are applied on each atom to steer the system to align the local order with a selected template, which is expected to drive the system quickly toward the basin representing the template. In metadynamics, history-dependent bias potentials are added on the fly to the underlying free energy landscape of the system, helping the system jump out of the current metabasin and explore nearby basins. Preliminary results with TAMD show that the effective cooling rate can already be reduced to 6.5×10^6 K/s. Currently, we have successfully constructed the free energy surface of pure metals including Cu and Al, and some typical Lennard-Jones systems, using conventional Steinhardt Q4 and Q6 parameters, and order parameters derived from cluster-alignment studies. We intend to extend such studies to multicomponent systems.

In addition, the order parameters are expected to describe the structural transitioning from amorphous to crystalline phases during crystallization. Then, one can use such parameters to study nucleation in supercooled liquids with metadynamics. One can also express various thermodynamic and kinetic quantities that govern the phase transformation in terms of such order parameters. Thus, accurate description and parameterization of both the extent and character of ordering is the critical link between atomistic behavior, transformation mechanisms, and the analytical descriptions of the thermo-kinetic landscape that are critical to prediction and realization of phase selection in highly driven systems and meso-scale modeling of the associated structures. Meso-scale approaches, such as phase-field simulation will be applied to investigate phase morphologies and competitive crystallization structures, guided mainly by experimental observation but using parameters obtained largely from atomistic modeling. We will continue to extend our experimental access to higher cooling rates using levitation, laser, and deposition processing, providing access to a broader transformation space and closing the gap with between experiments and molecular dynamics. In addition, we will use levitation (drop calorimetry) and DSC methods (9) to perform heat capacity measurements for Al-Sm and Cu-Zr alloys, over a range of compositions and temperatures.

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Mechanisms of crystallization in glass-forming liquids: interfaces, diffusion, and nucleation

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Program Scope

This program area is aimed at understanding the principal structures and mechanisms that govern crystallization in glass-forming systems. The large departure from equilibrium (i.e. undercooling) attainable in a glass forming system gives rise to a competitive crystallization scenario involving multiple highly driven phases. In this case, kinetic mechanisms related to interface structures, local order, and atomic mobility may govern the phase selection. In this subtask, we focus on these mechanisms of crystallization and their influence on transition dynamics. Efforts include experimental and computational methods to measure specific properties such as interfacial free energy, interface mobility, and diffusivity, and to examine the mechanisms and multi-scale nucleation and growth phenomena associated with crystallization.

Recent Progress

Molecular dynamics (MD) simulation can considerably contribute toward an enhanced understanding of the relation between the SLI free energy and bulk material properties. First, significant progress has been achieved in the development of methods to determine γ from MD

simulation (1-3). Second, it has been recognized that the interatomic potentials employed in classical MD simulation may be regarded as an additional "knob" that computational scientists may twist to sample a much larger set of materials than are observed in nature. In this study, starting from realistic semi-empirical potentials for Al and Na we developed sets of new potentials to explore the effect of liquid structure and latent heat on the SLI free energy. Next the SLI free energy was determined from MD simulation and the obtained data were compared with the Ewing relation



compared with the Ewing relation (4) which takes the form, $\gamma = C'_T \rho_s^{2/3} T_m \Delta S_m + C_O \rho_s^{2/3} T_m S_O$, where ΔH_m is the latent heat of melting, ρ_s is the atomic density in the bulk solid phase and S_O is the liquid excess entropy. The first term is the well known Turbull relation. The second term is related to the liquid structure, and our results (Fig. 1) have shown that this term is important, indicating that liquid structure must be accounted for in the interfacial free energy. Figure 1 also shows that the Ewing relation obtained from the bcc dataset also provides a reasonable description of the B2 data and therefore, can be used to predict the SLI free energy based on just easily accessible bulk material properties.

High-energy X-ray diffraction (XRD) measurements of undercooled, electrostatically levitated Ni₅₀Zr₅₀ liquid droplets revealed that the solidification pathway proceeded through the nucleation and growth of the metastable B2 phase, which persisted for several seconds before the appearance of the stable B33 phase (5). To explain the obtained results we determined the solid-liquid interface (SLI) free energies and the bulk driving forces for solidification for both competing phases from molecular dynamics (MD) simulation (see Fig. 3). For all temperatures approximately 100 K below the B2 melting temperature, the B2 nucleation barrier is always less than that for B33. Hence, our MD simulations suggest that the undercooled liquid is significantly more stable with respect to B33 than B2 for undercoolings comparable to the experimentally observed values. We will continue developing this approach to predict the phase transformation pathways when a glass is prepared from liquid (including glass formation itself).

Figure 2. (a) and (b) show SLI free energies (in mJ/m²) of the B33 and B2 phases as a function of the interface ²⁰⁰ inclination **n** in the crystal reference frame. (c), The -₂₀ nucleation barrier ΔG^* for these phases.



The structure and related phenomenology of solid-liquid interface (SLI) have been subjects of interest for decades (6-8). It is well known that the solid phase can induce layering in the liquid phase close to the interface along the direction perpendicular to the interface. However, ordering in the lateral direction and its effect on phase selection and growth kinetics is less understood. Using atomic mobility as a criterion to distinguish solid-like and liquid-like regions, we explore the phenomenology in the vicinity of a moving SLI. As an example, Fig. 3a shows a SLI between the Al₁₂₀Sm₂₂ "big cube" phase (BCP) at $t = t_0$. The atomic density along the perpendicular direction is given in Fig. 3b, where one clearly sees the induced layering on the liquid side for both SLIs. In our MD simulations, the BCP phase readily grows with a fairly fast growth rate of ~ 0.15 Å/ns. Such a high interface mobility is clearly reflected in the lateral plane ordering shown in Fig. 3c, the contour plot of the atomic density of the first layer on the liquid side (indicated by the arrow in Fig. 3b) at two instants - shortly before and after the interface moves to its current (t_0) position. At $t_0 - \Delta t$, some crystalline order that matches the BCP phase already emerges. At $t_0 + \Delta t$, although the interface has barely moved, the ordering in the liquid layer is strongly enhanced. Such rapid enhancement of crystalline order greatly facilitates continuous growth of the BCP phase.



Figure 3 (a) A snapshot of the BCP/liquid interface at $t = t_0$. (b) The density profile along the perpendicular direction for Al and Sm atoms. The dashed line indicates the interface position determined based on atomic mobility. The arrow indicated the first layer in the liquid phase. (c) The contour plot of the atomic density at t_0 - Δt and t_0 + Δt (Δt =1.2 ns).

Controlling transformation pathways in glass-forming liquids requires a comprehensive description of diffusivity, including the composition and temperature dependence of the associated kinetic arrest. In the computational study reported here (9), we examine atomic diffusion in Al-Sm liquids using ab initio molecular dynamics (AIMD) and determine the diffusivities of Al and Sm for selected alloy compositions. Through assessment of our AIMD result, we construct a general formulation for Al-Sm liquid, involving a diffusion mobility database that includes composition and temperature dependence. A Volmer-Fulcher-Tammann (VFT) equation is adopted for describing the non-Arrhenius behavior observed in the undercooled liquid, associated with enhanced local ordering. The composition dependence of diffusivity is found to be quite strong, even for the Al-rich region, contrary to the sole previous report (10) on this binary system. The model is used in combination with the available

thermodynamic database (11) to predict specific diffusivities and compares well with reported experimental data for 0.6 at.% and 5.6 at.% Sm in Al-Sm alloys (10, 12).

Future Plans

Future work will include using a suite of synthesis and processing techniques to systematically investigate phase selection response and to help direct our computational and analytical modeling efforts. Our goal is to extend our experimental observations of crystallization kinetics across all temperatures from the melting temperature (or liquidus) to below the glass transition temperature for the Al-Sm system. Methods will include levitation melting with free cooling, isothermal holding, splat cooling, and triggered growth; laser-trace melting/freezing; and magnetron sputter deposition.

MD simulations will be used to determine SLI free energies for stoichiometric compounds that compete to nucleate in the Al-Sm and Ni-Cu-Zr systems, investigate how the SLI free energy depends on temperature and interface curvature under conditions when

nucleation in fact occurs, investigate the role of point defects in nucleation and interface properties, study the relationship between physical properties and nucleation rates.

We will perform capillary tube liquid diffusion couple experiments to measure diffusivity in Al-Sm and Cu-Zr liquids. We will employ container-less processing techniques (electrostatic and electromagnetic levitation) to attain high degrees of liquid state undercooling for Al-Sm, Al-Tb, and Ni-Zr alloys. Controlled cooling of bulk droplets and triggered nucleation will be implemented to probe select domains of temperature and composition.

We also plan to extend the study of the interfacial ordering to other SLIs involved in the rich phase transformations of the Al-Sm system. This information, together with thermodynamic and kinetic analysis, will be used to evaluate the dominant factors that govern the phase selection in this prototypical system. In addition, our preliminary results of classical MD simulations indicate that an FCC Al seed can trigger the nucleation of a hexagonal phase. This provides an opportunity to study the mechanisms for heterogeneous nucleation.

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Metastable phase competition in highly undercooled metallic liquids and glasses

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Program Scope

Increasing technological demand for materials with new or enhanced functionality calls for expanding the set of accessible structures and chemistries. The methods of materials genomics enable the efficient identification of stable materials that may possess desirable properties, but metastable, multiphase, and defect-enabled states are excluded from such





searches, and predictions of stability or even metastability do not themselves provide a path to realization. Glass-forming metals offer a rich landscape of non-equilibrium states, both crystalline and non-crystalline, and far-fromequilibrium avenues to access them. This point is illustrated in Fig. 1, showing the extraordinary wealth of intermediate metastable structures that may appear during devitrification of an Al₉₀Sm₁₀ alloy. To understand phase selection dynamics in this motivating example and other similar scenarios, this task area aims to identify critical energetic and mechanistic links between thermodynamic quantities, interfacial structures, and the kinetics of transformation events that control phase competition in highly driven

systems. To meet this challenge, we combine synthesis techniques, X-ray diffraction (XRD), thermal analysis, electron microscopy, ab initio calculations, molecular dynamics (MD) simulations, and adaptive genetic algorithms (ADA) in an integrated scheme for materials discovery.

Recent Progress

For the Al-Sm system, the amorphous phases realized in melt spun ribbons (MSR) and magnetron sputtered thin films (STF) exhibit very similar structural order, as measured by their pair distribution functions (PDFs), yet these two structures devitrify following vastly different pathways (Fig. 1). When quenched from the liquid, the glass exhibits a polymorphic

transformation that results in the "big cubic phase" (BCP) a cubic $Al_{120}Sm_{22}$ phase with a lattice parameter of 13.904 Å, space group I m $\overline{3}$ m (No. 229) exhibiting 6 unique Wyckoff positions (1). The glass formed by sputtering develops pronounced compositional inhomogeneities before the formation of fcc Al and a "big hexagonal phase" (BHP), a hexagonal $Al_{20}Sm_4$ phase with space group No.182 (P6₃22) and with 5 Wyckoff positions (2). In both cases, the initial devitrifying transition consumes the entire sample, after which the resulting crystalline phases are observed to further transform, following strikingly different pathways. Both pathways



Figure 2 (a). A cubic $A_{160}Sm_{11}$ seed is put in contact with undercooled $Al_{90}Sm_{10}$ liquid at T = 800 K. (b). The liquid phase is fully grown into a defected cubic phase with the same composition in ~260 ns. (c) The XRD pattern of the as-grown phase shows excellent agreement with that of the experiments. Red circles in the inset of (c) show the antisite defects revealed in the MD simulations.

eventually converge toward the same phase composition (although the end states exhibit significantly different microstructures).

The first challenge in understanding the dynamics exhibited in this benchmark experiment is to solve for the complex unknown structures realized through these far-from-equilibrium processes. The approach we have developed (1, 2) effectively integrates: (i) lattice and space group information from high-resolution XRD; (ii) AGA analysis for structure determination (3); (iii) cluster alignment analysis (4) to reveal the underlying order; (iv) MD simulations for crystal growth; and (iv) Rietveld analysis to capture the defect distribution. Once the phases are identified and well described, we look for keys in the local structural that may be linked to the phase selection behavior. For example, we use our previously developed cluster alignment analysis to reveal the dominant local cluster motifs in the glass and identify particular motifs present in both the noncrystalline precursor and the metastable crystalline phases that initially form. We also use MD simulations to investigate the plausibility of the implied crystal growth scenario and compare the MD growth product with the experimental diffraction data, where site occupancies and defect structures are relevant or even critical.

Devitrification of glassy alloys is an ideal system with which to model systems far-from-

equilibrium. These systems can form complicated metastable structures often precipitate instead of simpler, more stable compounds which, as in this example are dependent on the material's synthesis. Navigating the phase selection process requires understating of the initial state of the disordered alloy and kinetically accessible states through the energy landscape. This in turn requires knowledge of the structure of the unknown compounds which do form. This also requires the ability to predict other metastable phases which may comptete. This is where the AGA is a critical tool since it provides a means of not only solving the structures of the unknown but observed compounds, but aids in determining the energy of competing strucutres. However, feedback with experiental data is crucial since the DFT can not easily address vacancies or antisite defects associated with partial occupancy of Wyckoff positions. Figure 2 illustrates how we determine the big cube phase that precipitates during the initial crystallization of melt-spun $Al_{90}Sm_{10}$ alloys. In Figure 2a, a parent big cube phase with the composition $Al_{60}Sm_{11}$ identified in AGA search is put in contact with undercooled $Al_{90}Sm_{10}$ liquid at T = 800 K. Figure 2b shows that the liquid is fully crystallized in about 260 ns. Containing multiple vacancies and antisite defects, the as-grown structure has a composition that matches the initial liquid phase. With no need for fitting occupancies or atomic positions, the XRD pattern of the as-grown structure shows excellent agreement with experiment (Figure 2c), indicating that the grown structure correctly captures the nature of the defects of the big cube phase. The same procedure is also applied to sole a big hex structure during the devitrification of Al₉₀Sm₁₀ alloys prepared by magnetron sputtering.(2)

Future Plans

We will continue to implement the AGA to solve unknown crystalline phases observed in our in situ diffraction experiments. In addition to predicting unknown crystal structures, AGA plays an important role in developing classical potentials. Due to significant spatial and temporal constraints of *ab initio* calculations, utilizing semi-empirical potentials still is necessary to fully describe the thermodynamic and kinetic properties of undercooled liquids and glasses. Based on our previous experience with Cu-Zr and Al-Sm systems, it is usually not sufficient to include only experimentally observed compounds in the potential development procedure. The AGA method readily identifies a series of metastable phases with relatively low formation energy. Although many of these phases are not observed experimentally, they provide useful information regarding packing motifs and bonding characters of the system. Inclusion of these extra phases has dramatically improved the reliability of potentials. Once all phases are described, the phase selection in the supercooled liquid can be studied by a combination of interrupted DSC, TEM, XRD and in situ SAXS and WAXS. The in situ SAX/WAXS experiments are particularly powerful for studying phase selection because SAXS probes the nano-scale topological/chemical rearrangements that precede devitrification while WAXS provides a direct measure of the crystal structures of nucleating phases.

We will consider the dynamics of both crystalline and non-crystalline phases that compete at high undercooling and give rise to complex transformation sequences involving multiple transient structures. First, we will compute the thermodynamic stability of specific crystalline phases using *ab initio* calculations and by using (quantum mechanics) corrected MD potentials in a statistical perturbation theory. These calculations provide important baseline information about ground state energies upon which to build a more complete thermodynamic description that accounts for entropy/temperature effects and additional thermodynamic features that complicate phase formation under realistic conditions. Second, we will utilize MD simulations to assess the role of solutes and packing effects at nonzero temperatures, providing the means to observe (through simulation) many realistic features of transformations. Third, we will employ a CALPHAD-style solution-based thermodynamic approach (5-7) for comprehensive thermodynamic modeling of the relevant multi-component multiphase systems and scenarios that govern transformations over broad composition and temperature ranges. Building on our prior treatment of driving forces for non-equilibrium solidification, these thermodynamic models will be used, along with diffusivity and interfacial properties (from experiments and MD simulations), to construct a self-consistent thermo-kinetic landscape that will enable analytical prediction and realization of phases and structures.

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Exploratory Materials Synthesis and Characterization

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Program Scope

We concentrate on exploratory synthesis and characterization of the new model materials of current interest in condensed matter physics. In addition, we often focus on advanced synthesis of known materials in order to enable important physical and structural investigations. We put strong effort in the discovery of new phenomena associated with correlated behavior of electrons in energy related materials. Most often materials are synthesized in the single crystal form since many observables of interest are tensor quantities and since this allows for the investigation of physical properties that are free of grain boundary influences. We use range of techniques suitable for exploratory materials synthesis and crystal growth: conventional arc melting and powder metallurgical techniques, solution methods, high temperature intermetallic, oxide, sulfide or salt fluxes, chemical vapor transport and deposition. Automated physical and structural characterization is the essential component of the lab. In order to optimize synthesis parameters, it is necessary to characterize structural and physical properties of materials. Quite often the same methods are used to investigate crystal structure, transport, thermodynamic and magnetic properties, sometimes at the extreme conditions. We perform high magnetic fields and low temperature measurements at NHMFL Tallahassee and HZDR Dresden. We also use EXAFS beamlines at NSLS and we are constantly engaged in the buildup of our synthesis and characterization capabilities. We currently pursue several research directions: Dirac and topological materials, quantum criticality and metal – insulator transitions. Our work enhances materials space available to BNL and other research groups. This program includes training of the next generation of scientists. Students from neighboring universities (Brown, Columbia, Johns Hopkins, Stony Brook) were being educated in materials physics, arts and crafts of crystal growth, materials synthesis and characterization.

Recent Progress

<u>Advances in synthesis/crystal growth.</u> High temperature metallic solutions are the method of choice for synthesis of many important correlated electron systems such as heavy fermions or iron based superconductors. Volatile and/or hazardous ingredients require the use of fume hoods. In order to be able to synthesize such materials in large size for neutron scattering, we have custom designed and installed two box furnaces with tall chambers that can accept large crucibles. Together with a centrifuge used for filtration, such system enables risk-free synthesis of large sample volumes. Furthermore, we have custom designed and installed a multi-zone



Fig. 1: Rotating gradient furnace in vertical position.

gradient furnace (Fig. 1) that has ability to rotate. In the horizontal position it will be used for vapor transport crystal growth in large volumes whereas in the vertical position it will be used to suppress evaporation in synthesis of samples with volatile ingredients such as chalcogenides.

Exploratory synthesis and characterization of novel materials. Highlights in FY13-15:

a) Large transverse magnetoresistance $(1.33 \cdot 10^5 \%$ in 2 K and 9 T field, and $4.33 \cdot 10^6 \%$ in 0.4 K and 32 T field, without saturation) and field-induced metal-semiconductor transition in NbSb₂ single crystal (Pub 1; Fig. 2). The sign reversal of the Hall resistivity and Seebeck coefficient in the field, plus the electronic structure reveal the coexistence of a small number of holes with high mobility and a large number of electrons with low mobility in distinct volumes of the electron and hole





pockets. The large effect is attributed to the change of the Fermi surface in magnetic field in addition to large magnetoresistance expected for high mobility metals.

b) Large thermoelectric power S due to electronic correlations in $RuSe_2$ (Pub. 2 – the first scientific publication of NSLS2). $RuSe_2$ is a semiconductor that crystallizes in a cubic pyrite

unit cell similar to FeSb₂, material with highest known thermoelectric power factor. Pyrites and marcasites (e.g. FeSb₂) both feature distorted octahedral coordination of Ru/Fe in the local structure. The Seebeck coefficient of RuSe₂ exceeds -200 μ V/K around 730 K (Fig. 3). Ir substitution results in the suppression of the resistivity and the Seebeck coefficient, suggesting the removal of the peaks in density of states near the

Fermi level and the importance of the electronic correlations in enhanced thermoelectricity. However, corner-



thermoelectricity. However, corner-sharing octahedra impede electric conductivity in RuSe₂ (Fig. 4).

<u>Advanced materials synthesis and crystal growth.</u> We have enabled several important STM, neutron and low temperature transport studies in the past two years. These include:

a) Direct verification that heavy fermion superconductivity stems from magnetically mediated Cooper pairing (Pub. 3). STM measurements on high quality single crystals of $CeCoIn_5$ elucidated the heavy-fermion band structure using quasiparticle interference imaging and

revealed quantitatively the momentum space structure of the *f*-electron magnetic interactions. Then, by solving the superconducting gap equations on the two heavy-fermion bands with these magnetic interactions as mediators of the Cooper pairing, a series of quantitative predictions were derived that are in agreement with the measured characteristics of CeCoIn₅.

b) In the cleanest samples of $Ce_{1-x}R_xCoIn_5$ (R = rare earth) the London penetration depth was consistent with the existence of line nodes in the superconducting gap. Substitutions of Ce with La, Nd, and Yb lead to similar monotonic suppressions of T_c. While La and Nd substitution leads to a dirty nodal superconductor response, Yb substitution suggests a change from nodal to nodeless superconductivity. This happens in the same doping range where changes of the Fermi-surface topology were reported, implying that the nodal structure and Fermi-surface topology are closely linked (Pub. 4).

c) Synthesis of large crystals of heavy fermion superconductor $CeRhIn_5$ enabled inelastic neutron scattering studies (Pub. 5). Preliminary results showed the breakdown of the singlequasiparticle description of the spin excitations in a helical itinerant heavy fermion magnet.

Future Plans

In the next period we will pursue several crosscutting directions. These include:

Dirac materials. In contrast to graphene and topological insulators, Dirac fermions in bulk Dirac materials¹ coexist with metallic states derived from other electronic bands at the Fermi level. Hence, due to electronic complexity, bulk crystals can be used to observe Dirac fermions in the environment of for example correlated quasiparticles, magnetic or superconducting orders. There are number of energy relevant materials where Dirac states have been observed, e.g. BaFe₂As₂ with spin density wave (parent compound of Fe-based high-Tc superconductors) or high performance thermoelectrics.²⁻³ In particular Weyl semimetals⁴ have recently raised considerable interest due to the monopol defects (sources and sinks) of Berry curvature – Weyl points in Brillouin zone. Since new bulk materials are necessary for large-scale power generation⁵ we will focus on exploratory synthesis of new bulk Dirac and Weyl materials in order to examine exotic quasiparticles, magnetic states, correlations and in particular thermoelectric⁶ properties. Furthermore, single layers of most such materials are likely to be produced by exfoliation (similar to graphene) due to 2D anisotropy and the interlayer binding energy which is similar to graphite.⁷

<u>Quantum criticallity</u>. Complexity of copper oxide materials implies that progress might be made by comparison with other exotic superconductors where competing interactions and phenomena - including recently observed charge fluctuations - can be observed at simpler or tunable settings. Examples include magnetic heavy fermion metals or charge density wave superconductors near putative charge quantum critical point (QCP). High quality single crystals of heavy fermion metals synthesized in our group enabled the Bogoliubov quasiparticle interference imaging of heavy fermion band structure and insight into dynamic susceptibility by inelastic neutron scattering (e.g. Pubs. 3,5). Having exposed magnetic mechanism of heavy fermion Cooper pairing, we will extend studies to heavy fermion systems with magnetic order. Similarly, some low dimensional chalcogenide materials or organic superconductors host features similar to putative charge QCP.⁸⁻⁹ We will search for new materials in this class and explore disorder effects.

<u>Heavy fermion-like states and metal-insulator transitions in d- electron metals</u>. We will explore materials with quasiparticle mass enhancement in narrow bands, similar to classical 4*f*-based compounds. Crystal structure types and materials include mixed anion oxychalcogenides; if the anions are from the different row of the Mendeleev chart, different size and ionic polarization may lead to layered structure due to ordered occupancy of different crystallographic sites.¹⁰

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Fundamental Studies of Plasma-Based Synthesis of Nanomaterials: A Joint Challenge for Plasma and Materials sciences

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Program Scope

The main goal of this project is to develop an understanding of the synergy of plasma and nanoscale material processes in carbon, boron nitride (BN), and hybrid B-C-N nanostructure synthesis, including but not limited to, fullerenes, nanotubes and nanofibers. The research program focuses on the integration of three areas:

1) Characterization of the plasma properties relevant to the synthesis processes;

2) Development and utilization of unique in-situ diagnostics of nanoparticles and nanostructures in the plasma and gas phase;

3) Development and validation of state-of-the-art nanomaterial simulations codes and relevant plasma models, which serves as a basis for integrated multiscale modeling of nanomaterial synthesis processes.

This research strongly emphasizes characterization of equilibrium and non-equilibrium plasmas at atmospheric pressure as well as synthesized nanomaterials. The focus is on the fundamental and interdisciplinary science associated with the synthesis of nanoparticles and nanostructures by atmospheric pressure arc discharges. We utilize a helium DC arc discharge with a vaporized anode at atmospheric pressure, or anodic arc, which has been successfully applied to the synthesis of a broad class of nanomaterials, including carbon nanoparticles and nanostructures and metal nanoparticles. The proposed research includes comprehensive experimental and theoretical studies of three major steps for arc synthesis of the above nanostructures: evaporation of anode materials; formation of atomic species and clusters; nucleation and growth of nanoparticles and nanostructures.

Our integrated approach for characterization of synthesis processes is: i) spatial and temporal measurements of plasma properties provide an input for modeling of atomistic processes; ii) modeling results of formation of nanoparticles and nanostructures are validated by in-situ diagnostics of nanoparticles and nanostructures synthesized in plasma; iii), synthesized

nanomaterials are extracted from the plasma during the arc and collected after the synthesis process. The extracted and collected materials are then characterized by ex-situ material evaluation to validate in-situ measurements and provide an additional input for modeling.

Recent Progress

The first year of the project has been devoted to comprehensive characterization of the carbon arc discharge as the source of nanoparticles, development of advanced *in-situ* diagnostics, and the selection of appropriate numerical tools for studies of synthesis processes in plasmas.

<u>Ablation and Deposition Processes in Arc Discharge for Nanosynthesis</u> Ablation of the anode electrode in the arc provides a feedstock of atoms and molecules for nanomaterial synthesis. Controlling of the ablation is important for overall control of the synthesis processes, including nucleation and growth of nanoparticles and nanostructures. Therefore, a considerable effort was made to study what arc parameters determine the ablation process. Experimental studies revealed that the nanosynthesis arc can operate in two different ablation/deposition

regimes depending on the anode diameter (Figure 1) [1,2]. One regime is characterized by the enhanced ablation rate, which is favorable for high yield synthesis of nanomaterials, because the yield of nanomaterials is determined by ablation rate. The second regime has a small and approximately constant ablation rate. Our recent studies demonstrated that the difference between these two regimes is determined by thin layers of space charge near the electrodes. These layers, so-called anode sheath and cathode sheaths, determine the amount of particles and heat fluxes to the electrodes. In the enhanced ablation regime, the electron heat flux to the anode is much higher than in the low ablation regime. A detailed theoretical description



Figure 1. Two main ablation modes of the arc discharge for synthesis of carbon nanotubes.

of the ablation process was developed and successfully explained experimental observations. The model includes coupled processes of ablation, deposition, latent heat released during the deposition, and thermionic emission from surfaces.

An important implication of these results is that for stable operation of the DC arc discharge, the cathode deposit must be conductive and therefore, for synthesis of non-conductive nanomaterials, the arc method needs to be modified to include, for example, forced convection of the flow in order to remove the non-conductive deposit or to use an AC arc discharge or electrodeless plasma, which would be less affected by the deposit than a DC arc. Moreover, the proposed physical mechanisms responsible for two ablation modes of the consumed anode can be relevant to other arc synthesis methods, including synthesis of metal nanoparticles.

<u>Development of advanced in-situ laser diagnostics of nanoparticles and related</u> <u>theoretical studies</u> We have developed a variety of diagnostic tools for characterization of plasma properties and in situ measurements of nanoparticles and nanostructures. These diagnostics include optical emission spectroscopy (OES), Coherent Rayleigh-Brillouin Scattering (CRBS), Laser Induced Fluorescence (LIF), Laser-Induced Incandescence (LII), as well as specially designed probe system for electrostatic extraction of nanoparticles.

The LIF will be a key diagnostic for measurement of precursor species to nanoparticle formation in the arc plasma, including carbon and boron atoms and ions, C_2 , C_3 , and metallic atoms and ions. An LIF diagnostic has been constructed and is being tested prior to initial measurements in the arc plasma.

The CRBS will be used to detect nanoparticles of less than 50 nm in the plasma. By exploiting the strong interaction between particles polarizability with intense laser fields, the CRBS will allow characterization of the type, size, density, and temperature of nanoparticles at various locations in the discharge. Unlike spontaneous Rayleigh-Brillouin Scattering and Mie scattering, CRBS relies on the creation of periodic gratings within a medium (plasma or gas) and provide much higher sensitivity and measurement resolution. According to modeling of expected CRBS signals, this diagnostic will have high sensitivity and should be capable of detecting spherical nanoparticles at concentrations as low as 0.005%. Higher sensitivity is expected for nanotubes. Assembly of the CRBS setup was completed and satisfactory performance was demonstrated by obtaining a single laser shot CRBS spectrum in air. A capability to measure well-characterized nanoparticles to test the system is being implemented.

As a part of the CRBS development, we conducted a comprehensive study of the dynamic polarizability of carbon nanotubes and fullerenes. The intensity of the CRBS signal in a gas with suspended nanoparticles is proportional to the polarizability of the nanoparticles. Thus it

is important to know the anisotropy of the polarizability tensor of the nanotubes and non-spherical fullerenes, and we have calculated the frequency-dependent electric polarizability and the photoabsorption spectra of carbon nanomaterials of different shapes and sizes in the frequency domain from static to the ultraviolet region of the spectrum. These linear response theory calculations have been based on time-dependent density functional theory (TDDFT) efficient Liouville-Lanczos using the approach implemented in the open source Quantum ESPRESSO (QE) package. The results demonstrate that CRBS will distinguish these structures through rotation of the polarization (Figure 2).

Another diagnostic system developed for in situ detecting of nanoparticles in plasma is LII. The LII is



Figure 2. Spontaneous Rayleigh scattering of nanoparticles computed from the TDDFT polarizability: The relative Rayleigh scattering intensity predicted for CRBS detection of different carbon nanoparticles with different aspect ratios.

capable to detect nanoparticles of larger than 10 nm using the incandescence signal after shortpulse laser heating. The LII was applied for detecting of nanoparticles in gas without plasma. Based on results of these experiments, we proposed and implemented improvements to the LII model for the determination of nanoparticles sizes. These improvements include heat transfer effects for complex nanostructures such as multi-walled nanotubes and also self-consistent description of charging effects with and without the presence of plasma. An important implication of these studies is that a large buildup of positive charge induced by thermionic electron emission due to irradiation by laser and/or plasma may induce disintegration of agglomerated nanoparticles and nanotube bundles when the electrostatic Coulomb repulsion force between nanoparticles is stronger than the van der Waals bond energies.

Future Plans

The project will follow the following main steps: 1) Comprehensive characterization of plasma arc environments (electron temperature and density, densities and temperatures of ionic, atomic and molecular species) for nanosynthesis of carbon, B-C-N and boron nitride nanotubes using OES, LIF and probe diagnostics; 2) Application of advanced in situ laser diagnostics including CRBS and LII, for detecting of nanoparticles in the plasma; 3) Advanced atomistic simulations of nucleation and growth of nanoparticles and nanostructures taking into account plasma effects such as heating and charging; 4) Development of reduced models for arc plasma growth of carbon and boron nitride nanotubes.

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Controlling graphitic substrates : metal intercalation, Li barriers in graphitic battery anodes and

graphene-based metamaterials. K.M. Ho^{1,2}, M.Hupalo¹, P. A. Thiel^{1,3}, M.C.Tringides^{1,2} and C. Z. Wang¹ ¹ Ames Laboratory, ² Department of Physics-ISU, ³ Department of Chemistry-ISU Ames IA 50011

I. Program Scope

The goals of this FWP are the controlled growth of nanostructured materials and their use to solve important technological problems. Novel properties emerge as the nanostructure dimensions are reduced, when compared to bulk materials, because boundary atoms have enhanced reactivity, and electron confinement plays a bigger role in defining the nanostructure properties. Utilizing our previous expertise, we plan to grow and use tunable metal nanostructures in three new directions, related to graphitic applications[1-3]. (i) Studying metal growth on graphene/graphite to modify graphene properties by intercalation.(ii) Measuring the controlling barriers for Li adatoms on graphene/graphite (adsorption, diffusion, and adatom-adatom interaction) to optimize Li storage in Li ion batteries (LIBs). (iii) Using our extensive expertise in preparing high quality graphene to apply it for Terahertz and Metamaterials applications, because of carrier tunability and reduced energy loss in graphene when compared to metals.

II. Previous work

Extensive work [4] to understand the metal/graphitic interaction (i.e. on graphene and graphite) has been carried out because this interaction is key to optimize metal contacts and high quality spin filters in graphene devices. In almost all cases studied, it was found experimentally and confirmed theoretically



Fig. 1. (a) and (b) STM images of Cu clusters on HOPG terraces. (c) (d) The coverage dependence and island size distributions indicate heterogeneous nucleation. Image size 250 x 250 nm²

that metal adsorption on graphene was 3-d, because the adsorption energy of a metal atom on graphene is smaller than the metal cohesive energy[4]. A standard method to study the grown morphology is to measure the nucleated island density n as a function of growth parameters (temperature T, flux rate F and coverage θ). From these measurements the diffusion and adsorption barriers are extracted. For graphene uses it is important to prepare low resistance metal contacts, so it is necessary to find ways to grow metals in 2-d (layer-by-layer).

It was also found that in some cases the standard scaling theory of nucleation for metals is not applicable, and long range repulsive interactions become increasingly important with deposited coverage. The role of even a small fraction of charged ions in the incident metal atom beam was shown to dramatically modify the nucleation during growth of Cu on graphite, as seen in fig.1 [5]. High island densities are observed which are incompatible with DFT calculations of the Cu diffusion barrier on graphite, found to be very low (~20meV). An alternative

explanation is deposition-mediated heterogeneous nucleation (due to the small fraction of Cu ions) was validated.

The important role van der Waals forces play in graphene stability and their role in metal/graphitic interactions was also clarified. Despite extensive work over many years in the literature related to metal growth on graphite, inconsistencies exist. We have critically reviewed the body of work [6], to be used as a guide by the whole community.

Graphene based spintronic devices require understanding the growth of magnetic metals like rare earth metals. The majority of the grown islands have triangular instead of hexagonal shapes, expected for hcp(0001) bulk Dy crystals[7]. By analyzing the island shape distribution and stacking sequence, it was deduced that the Dy islands have fcc(111) structure.

Using DFT, it was shown that QSE can induce oscillatory electrostatic potential because of workfunction differences in different terraces, parts of a Pb crystalline mesa grown over stepped Si(111). The electric field generated because of the electrostatic potential variation with terrace height, guides the positively charged Mg adatoms to terraces of low workfunction, thus resulting in a modulation of the adsorbed coverage with terrace height, as seen experimentally[8].

Recently Eu on graphene experiments indicate that metal intercalation is a very effective method for controlling island nucleation, because of spatial variation of doping, due to the intercalation[9]. A key question is mass transport, i.e., how atoms uniformly deposited on the surface populate only the pristine areas. Using DFT calculations, we show that due to the spatial variations of the doping an alternating lateral electric field (similar to the workfunction variation due to QSE discussed earlier) which guides adatoms from intercalated to pristine areas.

Classically, the onset of nucleation is defined in terms of a critical cluster of the condensed phase that forms from the gradual aggregation of randomly diffusing adatoms. Experiments in Pb/Si(111) at low



Fig.2 The 500 x 500 nm² growth of Dy on graphene/SiC (top). Higher nucleation is observed in the intercalated areas, as indicated in the schematic (bottom).

temperature have discovered a dramatically different type of nucleation, with perfect crystalline islands emerging "explosively" out of the compressed wetting layer[10]. The unexpectedly high island growth rates and the directional correlations in the growth of neighboring islands suggest that nucleation is a result of the highly coherent motion of the wetting layer over mesoscopic distances.

III. Future Plans

Based on the previous extensive expertise we have gained on the metal/graphitic interaction, we plan to pursue three new future directions.

IIIa. Controlling graphene properties by metal intercalation Surface-tailored intercalation of metals in layered compounds offers a versatile way to modify the surface properties of these materials. It has the potential to form 2-d metal layers that are chemically and mechanically protected, spatially localized, and functionally tailored. The combination of intercalated surface islands plus the modified overlayer could be useful in magnetic storage devices, micro- and nano-mechanical systems, and plasmonics In this FWP, we will focus on determining the basic factors that control surface intercalation of transition metals (TMs) and rare earths (REs), and on manipulating their chemical, spatial, and interfacial characteristics. Fig.2 shows how Dy nucleation is preferred on

intercalated (after heating to high temperature) than pristine graphene areas.

For layered carbon, there are essentially two classes of intercalation systems. One class is based on bulk compounds of graphite, which are well-known and diverse; in these the intercalant occupies the galleries between carbon sheets [11]. The other is based on supported graphene [12], where the intercalant is at or near the graphene-support interface. Many of the basic issues surrounding surface intercalation of TMs and REs, in both classes, have received little or no attention. These include the driving force, mechanism, and kinetics of intercalation; the spatial density and distribution of the intercalant; and the way in which intercalation changes surface properties of the graphene layer(s) on top. These basic issues will be investigated in the proposed work, simultaneously and synergistically with the exploration of practical methods for achieving patterned surfaces at the nanoscale to microscale. Graphene intercalation has been used mainly for doping, but the amount and distribution of intercalant atoms has not been studied systematically.

Intercalation involves complex diffusion processes along and between layers, and the stable states depend sensitively upon van der Waals interactions. The microscopic mechanisms and dynamics of these processes are not well understood. Several mechanisms for spontaneous surface intercalation under supported graphene have been considered in the literature, with varying levels of justification: diffusion from edges of graphene flakes toward the interior [13,14]; penetration at nanoscale features such as
domain boundaries or nanoscale cracks [13]; intercalation though localized or point-like defects [9,13]. Overall, the details of the intercalation pathways are still under much debate.

Compared with surface intercalation beneath supported graphene, there has been almost no exploration of surface intercalation on graphitic substrates. Moreover, the kinetics of surface intercalation, with associated diffusion pathways and diffusion barriers of metal atoms within the interstitial gallery, have not been probed. We will perform experiments and theoretical calculations to elucidate the details of intercalation and diffusion pathways and kinetics.

III.b Measuring key atomistic Li barriers in graphene/graphite for optimal LIB operation. Inhomogeneity and disorder are intentionally introduced in LIBs to enhance charge capacity (i.e. increase number of binding sites) but their detrimental role in slowing Li diffusion and reducing recycling capacity is not fully characterized. The interplay between effects related to tuning these barriers is critical in determining battery performance[15-17]. We plan to measure/calculate these key barriers on benchmark graphitic surfaces and use them as reference parameters to be compared with the corresponding barriers in real LIBs. The comparison of benchmark to real barriers will clarify the range over which real barriers can be mutally tuned for optimal battery performance.



Fig. 3 $3.7x3.7nm^2$ showing the graphene lattice with the $6\sqrt{3}$ periodicity (bright blobs).

Very limited work exitsts in the literature related to Li growth on graphitic surfaces and few theoretical estimates of the adsorption and diffusion energy barriers based on DFT have been carried out [16]. Since these barriers are the important ones controlling the Li storage and recycling in LIBs we will study adsorption, nucleation, and diffusion of Li on graphitic substrates over a wide range of sub-monolayer coverages. Very low coverage (~0.01ML) experiments will be used to measure the single adatom diffusion barrier E_d and the adatom dipole interaction ΔE from the spatial distribution of the Li adatoms. Independently, in other experiments, we will measure the nucleated island densities as a function of growth parameters (temperature and flux rate). Using the scaling theory of nucleation[18], E_d and cohesive energy E_c will be extracted to be compared with the results obtained from the adatom distributions. We will use our expertise in measuring chemical diffusion $D(\theta)$

as a function of coverage using the STM-based current fluctuation method because the Li recycling involves diffusion in the presence of other Li adatoms. We will employ temperature programmed desorption (TPD) to measure desorption of Li from graphite and determine the adsortion energy E_a . In TPD, the rate of desorption (proportional to pressure) is measured as a function of temperature. The current theoretical estimates for the relevant barriers are adsorption energy $E_a=1.08\text{eV}$, the diffusion energy $E_d=0.32\text{eV}$ and no estimate of the Li-Li interaction. Our experimental measurements will be compared to these preliminary estimates.

Besides the submonolayer coverage experiments we will look at the multi-layer growth for Li to verify if it is 3-d, similar to the growth mode for the other metals studied by us [4]. Earlier LEED work has shown Li non-crystalline cluster formation on top of graphite, and upon heating to 200 °C, diffusion into the bulk. On the other hand, ARPES studies of graphene grown on SiC have shown room temperature Li intercalation, from changes in the graphene electronic band structure. The transfer of Li into the bulk is the crucial process controlling the Li amount that can be stored. Our experiments will image the grown Li multilayer morphology, determine the temperatures where the Li 3-d clusters become crystalline, determine the onset of Li diffusion into the bulk as a function of Li deposited amount and temperature, and identify possible differences between multilayer Li growth on graphene versus graphite. III.c Growth of High Quality Epitaxial Graphene for Metamaterials To prepare well-characterized epitaxial graphene (EG) grown on SiC of the highest quality (fig.3) and to use it for plasmonics and MM applications [19]. The FWP has extensive experience in preparing large domains of defect-free EG of uniform thickness (single, bilayer, intercalated graphene). Besides the advantage of plasmon confinement within a single atomic layer, graphene is less lossy than metals and its carrier density can be easily tuned, either by gating or by doping. This tunability offers many different ways to control the EM response and establishes graphene as a promising material for Terahertz (THz) applications.

In addition, a new approach is planned to isolate graphene from substrate excitations (that can shorten plasmon lifetime) ,i.e., by intercalating randomly distributed gas adatoms between graphene and the substrate [20]. Gas adatoms will be also used to decouple the different layers in stacked graphene (i.e. a universally sought structure because it will increase conductance without compromising the single layer graphene advantages). Intercalation offers another possibility to confirm an outstanding prediction that stacked and decoupled graphene layers can be used to tune plasmonic resonances over a wider frequency range and with much higher dynamic range for the resonance amplitude. The accurate knowledge of the graphene conductivity will be used to design and fabricate patterned graphene samples with improved MM properties for the frequency range of interest.

We plan to use this expertise in collaboration with the MM FWP to prepare well characterized samples with enhanced performance for plasmomics and THz applications. The design and modeling of novel MM structures requires an accurate knowledge of the graphene conductivity $\sigma(\omega)$. Conflicting values exist in the literature for the model parameters, the Drude weight α and the collision frequency γ . Partially this is due to the low quality of the graphene samples but our ability to grow defect-free graphene and to introduce disorder in controlled ways will measure how plasmon lifetimes depend on disorder and clarify the contradictory results.

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Growth Mechanisms and Controlled Synthesis of Nanomaterials (ERKCS81): Synthesis of Two-Dimensional Metal Chalcogenides by Laser Vaporization and CVD

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Program Scope

The overarching goal of the research program is to understand the link between the growth mechanisms and the resulting structure of nanoscale materials. The emphasis is on the development of real-time methods to induce and probe chemical and physical transformations away from thermodynamic equilibrium, in order to controllably synthesize nanomaterials with enhanced properties resulting from metastable structures. The approach relies on correlating the real-time diagnostic measurements with predictive theoretical methods and post-growth characterization by imaging, spectroscopy, and atomicresolution analytical electron microscopy, to develop a framework for the deterministic synthesis of nanomaterials with desired properties.

Specific aims of the program are:

- (1) To reveal the kinetic pathways by which "building blocks" are involved in the growth of nanostructures through the development of real-time measurement approaches and modeling.
- (2) To understand the special role of nonequilibrium growth environments in capturing metastable phases and structures with novel nanoscale properties through the development of new synthesis and processing approaches incorporating in situ diagnostics.
- (3) To understand the atomistic interactions governing the design and synthesis of nanostructures with specific configurations and functionalities through predictive theory and associated experiments.

Recent Progress

Layered materials, grown as monolayers or few-layered two-dimensional (2D) crystals, are emerging as novel new materials for optoelectronic applications. 2D nanosheets of transition metal dichalcogenides (TMDs, with the stoichiometry MX₂ with metals such as Mo, W, Ti, Zr, etc. and X=S, Se, Te) and their heterostructures offer an exciting new platform for potential applications of these materials in optoelectronics and nanophotonics as well as exquisitely well-described interfaces for combined experimental and theoretical studies. The fundamental optoelectronic properties of 2D nanosheet heterostructures originate from the sensitive interplay between van der Waals (vdW), charge transfer (CT), and orbital hybridization (OH) interactions at atomic-scale interfaces. These same vdW/CT/OH interactions also govern the synthesis of these materials, determining how strongly atomic, molecular, and cluster "building blocks" interact with the substrate (either epitaxy or vdW-epitaxy) and each other.

Recently we have employed both chemical vapor deposition (CVD) and pulsed laser deposition (PLD) to explore the nucleation and growth processes of a variety of 2D crystals (e.g., GaSe, MoSe₂,

 WS_2 , WSe_2 , etc.) and their heterostructures (both lateral and vertical) on various substrates. Understanding the mechanisms by which 2D nanomaterials grow on different substrates is essential in order to synthesize these nanomaterials with well-defined numbers of layers, large crystalline domains, and ordered stacking required by many potential applications. Synthesis of 2D nanomaterials, e.g., metal chalcogenide nanosheets, have common challenges that include: 1) controlling nucleation density,

domain orientation, and number of layers, 2) rapid growth over large areas, and 3) growth of large crystalline grains. To address these challenges development of *in situ* diagnostic approaches for controlling and understanding growth mechanisms of these materials are required. Here, we discuss our specific results on 2D metal chalcogenides growth by CVD on SiO₂ substrates and graphene, which demonstrates that the interlayer coupling including charge transfer is responsible for the preferred orientations observed among the bilayer crystals and heterostructures. In addition, we show how the digital delivery of precise amount of sulfur atoms by PLD with super-thermal kinetic energies were used to control sulfurization (doping) for either alloying or total conversion of MoSe₂ to MoS₂ to form lateral heterojunctions.

Van der Waals epitaxial growth of 2D crystals by a chemical vapor deposition method

vdW heteroepitaxial growth of 2D crystals is attracting more and more interest because self-assembly processes during growth should result in reproducible, energetically-preferred interlayer orientations, more seamless stacking, and clean, sharp interfaces. Although the interactions with the substrate in van der Waals type epitaxial growth are much weaker than

in standard epitaxy, such interactions can still have a strong influence on the growth and properties of 2D materials. Here we investigate the CVD synthesis of layered 2D metal chalcogenide (GaSe, MoSe₂) nanosheets on various substrates to characterize the growth environment and understand the preferred orientations of 2D atomic layers on substrate by vdW epitaxy. The size, density, shape, thickness, and uniformity of the 2D GaSe crystals on SiO₂ were shown to be controllable by growth duration, growth

region, growth temperature, and argon carrier gas flow rate. The argon carrier gas flow rate was found to play an important role in controlling the thickness of the resulting crystals. At low carrier flow rate, uniform, large (up to ~60 μ m in lateral size), single-crystalline, triangular monolayer GaSe crystals were grown on SiO₂ substrates, with the layer number controlled by diffusion through the boundary layer.¹ However, at higher carrier flow rates, monolayer GaSe growth changed reproducibly to bilayer GaSe crystals (0° or 60° interlayer rotations) in a "layer-plus-island" mode.² Theoretical analysis reveals that the the preferred orientations among the bilayer GaSe crystals were determined by the



Figure 1 Revealing the atomic resolution structure of bilayer GaSe crystals and GaSe monolayer on graphene by growth directly on TEM grids. BF-TEM images of (a) bilayer GaSe crystals with AB stacking pattern and (b) GaSe on graphene with 10.9° lattice rotation. Insets are SAED patterns from the area indicated by solid circles. Corresponding ADF-STEM images of (c) the bilayer and (d) heterostructure. Insets are magnified images and intensity profiles along the solid lines.



Figure 2 Schematic illustrations of vdW heterostructure unit cells (supercells) constructed by 1L GaSe epitaxy on 1L graphene with interlayer lattice rotations of 10.9° and 19.1° , respectively.

energies of the interlayer coupling. In order to explore the atomistic effect of substrates on the vdW epitaxial growth of 2D crystals, GaSe atomic layers were grown on transferred CVD-grown graphene

(Gr).³ GaSe crystals are found to nucleate predominantly on random wrinkles or grain boundaries of graphene, share a preferred lattice orientation with underlying graphene, and grow into large (tens of microns) irregularly-shaped, single-crystalline domains. The domains grow with triangular edges that eventually merge into large single crystals. Electron diffraction revealed that the GaSe domains are predominantly oriented with a 10.9° interlayer rotation with the underlying graphene (Fig. 1c). Theoretical investigations of the interlayer energetics reveal that this interlayer rotation is the most energetically preferred vdW heterostructure (Fig. 2) with the smallest supercell (a non-intuitive orientation that minimizes interlattice atomic mismatch). In addition, strong charge transfer in these GaSe/Gr vdW heterostructures is predicted, which agrees with the observed enhancement in the Raman E^{2}_{1g} band of monolayer GaSe and highly-quenched photoluminescence compared to GaSe/SiO₂. This result reveals that the charge transfer of 2D crystals and other chemical/physical interactions with the substrate such as the electronic properties of substrates (e.g., metal, insulator, semiconductor) govern the growth processes.

To provide atomistic understanding of 2D material growth, and especially how monolayers and bilayers of 2D metal chalcogenides nucleate and grow, we developed synthesis methods for vapor phase growth directly on Transmission Electron Microscopy (TEM) grid substrates. Various 2D metal chalcogenides, including GaSe, MoS₂, MoS₂, WS₂, and WSe₂ single crystal islands were grown on SiO₂/Si, graphene, and SiO₂ membrane substrates. On membranes of SiO₂ or transferred graphene on grids, atomic-resolution Annular Dark Field Scanning Transmission Electron Microscopy (ADF-STEM) and Bright Field TEM (BF-TEM) was used to reveal the structure of single-crystal monolayer¹, atomic stacking in bilayer GaSe crystals² and GaSe/Gr heterostructure³ (Fig. 1). We revealed the edge structures of the crystals, and learned that interlayer stacking controlled the bilayer crystal structure and the orientation of epilayers, which consequently determines the crystal's optoelectronic properties. Our theoretical analysis has shown that the interlayer coupling is highly correlated to the local crystal symmetry, which is responsible for the preferred orientations observed among the bilayer crystals and heterostructures.

Isoelectronic doping of 2D transition metal dichalcogenide crystals for heterostructures

Doping is one of the essential technologies needed in various applications of 2D materials. Isoelectronic doping (substitutional or alloy) has the effect of mitigating the effects of deep traps, unintentional impurities, and dislocations in 2D Isoelectronic materials. doping introduces trapping potentials in the lattice due to the difference of electronegativities between host and impurities to tune the bandgap of 2D crystals. However, stable and highly-efficient doping techniques still remain a challenge. Pulsed laser deposition has long been renowned for its ability to transfer stoichiometry from targets to substrates, for its digital delivery of precise quantity of reactants, and for the inherent kinetic energy in the process to enable non-equilibrium growth conditions. In recent work. we demonstrated that PLD conditions tailored to deliver stoichiometric UNPs of 'amorphous' GaSe



Figure 3 Atomic resolution ADF-STEM image of (a) Wdoped MoSe₂ (b) the junction between MoS₂ on the left, and MoSe₂ on the right obtained by converting monolayer MoSe₂ using S atoms deposited by PLD. (c) Complex, scalable arrays of semiconductor heterojunctions promising building blocks for future electronics—were formed within a 2D monolayer of MoSe₂ by converting lithographically exposed regions to MoS₂.

or $MoSe_2$ to hot substrates could directly synthesize metal chalcogenide (GaSe, $MoSe_2$) nanosheets.^{5,6} In addition, we explored pulsed laser vaporization as a nonequilibrium method to effect substitutional doping and conversion of existing 2D crystals.

We have recently demonstrated the isoelectronic doping of 2D crystals of MoSe₂ using PLD-generated laser plumes (of sulfur in vacuum) and by CVD methods (using tungsten from WO₃). The sulfur incorporation efficiency is related to the kinetic energy of the arriving sulfur species. Through the digital delivery of a precise amount of sulfur atoms with super thermal kinetic energies during the doping process, the controlled sulfurization for either alloying or total conversion of MoSe₂ to MoS₂ were achieved. Using well-developed and scalable photolithography processes, a variety of patterns exposed to the sulfur plume produced predefined arrays of lateral MoS₂/MoSe₂ heterojunctions within a single monolayer in a single processing step. Figure 3 shows an atomic-resolution ADF-STEM image of the W-doped MoSe₂ and the junction between the converted (left, MoS₂) region and a lithographically-protected (right, MoSe₂) region of the original 2D crystal. PLD therefore provides a controllable and efficient way to explore doping kinetics through the digital delivery of precise quantities of the dopant.

In summary, 1) we employed graphene as a template for suppressing other metastable orientations during nucleation for large area single crystal GaSe growth by vdW epitaxy. Our experimental and theoretical analysis have shown that the interlayer coupling is highly correlated to the local crystal symmetry, which is responsible for the preferred orientations observed among the bilayer crystals and heterostructures. 2) Pulsed laser evaporation doping of 2D materials provided a controllable and efficient way to explore the doping dynamics through the digital delivery of precise quantities of the dopant. Understanding the mechanisms by which 2D crystals grows on different substrates or by doping is essential in order to synthesize 2D crystals with tuned bandgaps, the well-defined numbers of layers and ordered stacking required by many potential applications.

Future Plans

We have demonstrated 2D materials were controlled synthesized from the vapor transport process by using CVD and PLD, however, the detailed growth mechanisms have not yet been well understood. We propose to use in situ, time-resolved diagnostics of both the growth environment and the crystal growth to understand the kinetic pathways and reactive intermediates for 2D TMD nucleation and growth. For example, our preliminary results show the shapes of 2D crystal are determined by difference in the growth rates for zigzag and armchair edges. We are exploring a novel growth-etch-regrowth method for 2D GaSe crystals combined with in situ Raman scattering, time-resolved reflectivity, and direct optical and TEM imaging to reveal nucleation and growth kinetics. With real-time control, we will be able to stop and restart growth under different processing conditions to assess and adjust etching rates, understand how the competition between etching and growth processes shape the evolution of crystal edges for a comparison with classical theories (e.g., kinetic Wulff construction vs. Ehrlich-Schwoebel step barrier growth mechanism). As for the exploring the doping mechanism, we will use imaging and ion probes to measure the kinetic energy of the sulfur plume, and with discrete laser pulse-by-pulse delivery of sulfur to understand the kinetics and flux-dependence of the MoSe₂ to MoS₂ conversion process using in situ Raman spectroscopy, OAS and PL to characterize the crystal structure vibrational modes and band gap evolution vs. pulse number and time. With these in situ capabilities we propose to isolate metastable states with intermediate band gaps in the MoSe_{2-x}S_x system for examination by ADF-STEM and associated atomistic modeling of the conversion process.

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Growth Mechanisms and Controlled Synthesis of Nanomaterials (ERKCS81): Modeling and Characterization of Ultrasmall Nanoparticles

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Program Scope

The overarching goal of the research program is to understand the link between the growth mechanisms and the resulting structure of nanoscale materials. The emphasis is on the development of real-time methods to induce and probe chemical and physical transformations away from thermodynamic equilibrium, in order to controllably synthesize nanomaterials with enhanced properties resulting from metastable structures. The approach relies on correlating the real-time diagnostic measurements with predictive theoretical methods and post-growth characterization by imaging, spectroscopy, and atomicresolution analytical electron microscopy, to develop a framework for the deterministic synthesis of nanomaterials with desired properties.

Specific aims of the program are: (1) To reveal the kinetic pathways by which "building blocks" are involved in the growth of nanostructures through the development of real-time measurement approaches and modeling, (2) To understand the special role of nonequilibrium growth environments in capturing metastable phases and structures with novel nanoscale properties through the development of new synthesis and processing approaches incorporating in situ diagnostics, and (3) To understand the atomistic interactions governing the design and synthesis of nanostructures with specific configurations and functionalities through predictive theory and associated experiments. Theoretical methods are used to understand fundamental mechanisms of synthesis in order to guide the formation of nanostructures tailored to enhance energy storage, catalysis, thermal management, and photovoltaics in support of DOE's energy mission.

Recent Progress

Understanding atomistic interactions governing the synthesis of nanostructures with specific configurations and functionality: titanium oxide nanoparticle "building blocks" and "black TiO₂"

Ultrasmall (~ 3 nm diameter) nanoparticles of TiO₂ were formed by pulsed laser vaporization of TiO₂ targets in oxygen and used as "building blocks" as they annealed under different conditions to transform into different crystalline phases and structures.¹ The example of "black" TiO₂ demonstrates that the synthesis pathways have a critical influence on the formation of properties and functionality. Black and other forms of reduced TiO₂ are interesting because of the band gap reduction that is associated with the color change that occurs when ultrasmall nanoparticles (UNPs) synthesized by pulsed laser vaporization are annealed in a highly reducing atmosphere. Characterization by atomic-resolution TEM imaging shows that although the as synthesized UNPs are clearly identifiable by their shape, Selected Area Electron Diffraction (SAED) reveals that they lack coordinated crystalline order.

However, recently we have examined *single* as-synthesized UNPs with sub-nm spatial resolution employing Nano Beam Electron Diffraction (NBED) and electron energy loss spectroscopy (EELS). As

shown in Figure 1, regions of nanoparticle exhibit the diffraction spots indicating that amorphous TiO₂ the nanoparticle already has TiO₆ octahedra, but randomly ordered. These measurements within single, а computationally-tractable

nanoparticle. give an opportunity to develop an understanding of the evolution crystalline order and of energetics within a single, "building metastable UNP block" as it is annealed to acquire an energeticallyphase. preferred crystalline Understanding phase of transformations on the singlenanoparticle level is an essential first step toward a



Figure 1. Sub-nm spatial resolution electron diffraction and EELS reveal regions of crystalline order within a single 3 nm TiO_2 'amorphous' nanoparticle. Such measurements provide "descriptors" for crystal structure and electronic structure that can be calculated and compared with theoretical simulations of possible atomic configurations within a single UNP "building block".

model for the assembly of UNP building blocks to larger nanostructures. NBED and EELS appear to be excellent "descriptors" to correlate experiment and modeling.

Development of Hybrid Optimization Algorithm for the Identification of Ti_nO_{2n} Nanoparticle Systems

We are developing a hybrid optimization algorithm to theoretically explore atomic structure configurations of TiO_2 nanostructures.² Our ultimate goal is to theoretically simulate experimentally synthesized ultrasmall nanoparticles, and to identify the structural characteristics and energy landscape



Figure 2. Energy distribution of identified $(TiO_2)_{50}$ particles using the hybrid optimization algorithm. Spatial distributions of representing structures at the peak locations are shown in the inset. The right panel highlights the polygonal units of a nanoparticle.

of plausible UNP $(TiO_2)_n$ clusters (*n*=1-1000). Much of the literature on identification of (meta)stable Ti_nO_{2n} nanoparticles using evolutionary optimization algorithms utilizes Genetic Algorithm, which typically requires discretizing the search space, or simulated annealing, which does not utilize a population-based search. The use of newer, more powerful evolutionary algorithms remains to be explored. Furthermore, the effectiveness of optimization algorithms is often gauged by their ability to identify the global minimum energy structure, or their ability to reproduce an empirically observed structure with some frequency. Such assessments validate an algorithm's performance against its stated goal, but inhibit the comparison of algorithms developed to meet different goals.

Our proposed hybrid algorithm includes a modified differential evolution algorithm, and a permutation operator to perform global optimization on a set of randomly generated structures. This set is then refined using a Broyden-Fletcher-Goldfarb-Shanno Quasi-Newton algorithm, which calculates the gradient of the potential energy based on the well-established force field potential [3] for the system, with respect to atom positions only. We confirmed consistency with numerical results found in the literature for stable clusters (n<20). The smallest structures are either metastable (kinetically accessible) or near the global minimum. This scheme defines effectiveness as the ability of an algorithm to produce a set of structures whose energy distribution follows the regression as the number of Ti_nO_{2n} increases without specifying an exact distribution to allow for flexibility between approaches.

Figure 2, as an example, presents the distributions of $(TiO_2)_{50}$ structures in the energy space, obtained from our approach. Two main peaks in the distribution plot represent condensed phase and gas phase at the low energy and high energy, respectively. The results indicate that our stochastic approach mimics the synthesis experimental conditions, such that those two physical phases are identified without imposing any constraints during the global optimization search. Further analysis discovers a strong correlation between the density of polygonal units and the structural stabilities, that is, as the polyhedral



Figure 3. – Illustration of a theory-experiment combined scheme proposed in this project. Theoretical approach combines the development of global structure search, force field, and first-principles approaches. Experimental techniques are materials synthesis using various techniques and materials characterization using NBED and EELS, etc. The goal of this approach is to identify experimentally synthesized UNPs, and to identify their structure evolution pathways, by implementing unique theoretical approaches. [unpublished]

unit density gets higher, the structural stability increases. The right panel of Fig.2 illustrates the location of the polyhedral units of one of the found structure. We further identified a set of global or metastable configurations of Ti_nO_{2n} up to ~100, where the energy of the nanoparticles approach to that of bulk value as the system size increases. Combining first-principles theory we analyzed electronic properties of some of the obtained structures, which will be experimentally verified.

Figure 3 summarizes our current and future approaches that combine atomistic theory and synthesis and characterization experiment. Based on the basic information from experiment, such as composition and sizes, we have constructed theoretical model/tool to efficiently explore configuration space of UNPs. We expect the calculations to predict statistics for the occurrence frequency of the particles with different energetic stabilities. We have already performed some analysis of a large distribution of UNPs, where their total energies are described using relatively affordable force field approach. Our analysis approaches include basic structural and electronic properties, where more accurate and computationally much more expensive, quantum mechanical description is necessary. In the course of the quantum mechanical analysis, we will have a feedback loop with experiment that analyze electronic and structural properties of UNPs using characterization tools such as EELS and NBEDs. Eventually the theory-experiment loop will continue in identifying structure evolution pathways and suggesting new experiments to refine the theoretical modeling.

Future Plans

Ultrasmall nanoparticles (UNPs) show very unique features and they can be used as building blocks for synthesis of other nanoscale materials. Therefore, identifying and understanding their structures, phases, and interactions are central to control synthesis of nanowires, nanoparticle assemblies, thin films, and 2D nanosheets from the UNPs. To address this challenge, our theoretical approach to explore a configuration space of molecules by combining efficient total energy calculations and computational optimizer algorithm will be further developed and applied to the UNPs building blocks. Once those intermediates or nanoclusters are identified for a given experimental condition, detailed analysis of their structural and electronic properties will be performed using state-of-the-art first-principles approaches, where theoretical results will be compared with experimental data such as HRTEM, XRD, EELS. Then, we will move forward to model processes of doping of UNPs and process of forming larger nanostructures through melting and sintering UNPs at high temperatures.

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University Grants' Abstracts

Direct Oriented Growth of Armchair Graphene Nanoribbons on Germanium

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Program Scope

The overarching objective of the present grant is to learn how to synthesize both monolayered and multilayered nanostructured graphene materials without highly detrimental etch-induced disorder and with exceptional properties – from the bottom-up via chemical vapor deposition (CVD). The proposed research is being carried out in 4 thrusts:

- A. Understanding the growth of unpatterned graphene on metal surfaces via CVD;
- B. Constricting the growth of monolayered graphene on the nanoscale from the bottom-up;
- C. Templating nanostructured multi-layered graphene and graphite from the bottom-up; and,
- D. Exploiting metal surfaces to catalyze the repair of the defective edges of nanostructured graphene.

Recent Progress

Progress in two areas will be highlighted.

1. Breakthrough in substrate-driven template-less graphene nanoribbon synthesis.

We have discovered an exciting, unexpected, powerful new route for synthesizing graphene nanoribbons. The synthesis overcomes roadblocks that have plagued the nanoribbon field and is performed on a Ge(001) surface.[1]

Overview: Graphene can be transformed from a semimetal into a semiconductor if it is confined into nanoribbons narrower than 10 nm with controlled crystallographic orientation and welldefined armchair edges. However, the scalable synthesis of nanoribbons with this precision directly on insulating or semiconducting substrates has not been possible. We have realized the bottom-up synthesis of graphene nanoribbons on Ge(001) via CVD. The nanoribbons are self-aligning, are self-defining with predominantly smooth armchair edges, and have tunable width to < 10 nm and aspect ratio to > 60.



Fig. 1. Graphene nanoribbon CVD on Ge(001). (A) Crystal aspect ratio diverges as growth rate slows. (B) Ribbons selfalign along crystallographic directions of Ge. (C) STM image of 10 nm wide nanoribbon on Ge. The features on the Ge surface are oxidation features arising from transfer from CVD to STM chambers in ambient.[1]

We have learned how to drive graphene crystal growth on Ge(001) with a giant anisotropy. At a vanishingly small growth rate, at high hydrogen partial pressure, and by using CH₄ as a precursor, graphene crystals evolve anisotropically, resulting in nanoribbons with high aspect ratio and smooth, straight edges. We find that the one-dimensional nature of growth is insensitive to the bulk Ge dopant concentration $(N_{Sb} < 1.5 \times 10^{18} \text{ cm}^{-3}),$ Ge surface treatment prior to synthesis (OH, H, and Cl functionalization), and annealing time before growth. Nanoribbons are not observed on Ge(110) nor Ge(111) under any growth condition.

Low-energy electron microscopy (LEEM) and diffraction (LEED), in collaboration with the group of Richard Martel at the University of Montreal, have been used to determine the orientation of the graphene lattice with respect to the underlying Ge and with respect to the ribbon edges (Fig. 2A-D). The overlaid LEED patterns in



Fig. 2. Graphene nanoribbon CVD on Ge(001). (A-D) LEEM characterization of graphene nanoribbons on Ge(001). (A) Overlaid LEED patterns showing the {01} (cyan), {02} (brown), and {11} (magenta) diffracted beams from the unreconstructed Ge(001) surface. (B) LEED pattern obtained showing the purple and orange families of graphene orientations rotated by 30° and the splitting of the spots by 6° within each family. Arrows indicate the Ge<110> directions as shown in A. (C) Superposition of dark-field images of graphene nanoribbons on Ge(001) in which green, blue, and red channels of the image originate from the {01} graphene diffraction spots circled with the same color in B. Scale bar is 1 μ m. (D), Schematic depicting the four nanoribbon orientations that are detected.[1]

Fig. 2A taken at 121 eV and 135 eV establish the Ge[110] and [$\overline{1}10$] directions. The LEED pattern in Fig. 2B obtained at 67 eV shows that the graphene lattice primarily exists within two families of crystallographic orientations, denoted by the orange and purple hexagons. Both of these families of ribbons have edges that are macroscopically aligned with the armchair direction of graphene. This edge orientation is unique in that graphene crystals grown on Cu and Ni typically have edges that are aligned along the zigzag direction of graphene. Within each family, there are two unique graphene orientations that are rotated $2.9 \pm 0.4^{\circ}$ (~ 3°) relative to the Ge<110> directions, as indicated by the diffraction spots belonging to the orange family that are circled in red and blue in Fig. 2B. These nanoribbon orientations are depicted in Fig. 2D. Darkfield imaging in Fig. 2C indicates that some of the ribbons are single-crystalline, corresponding to either the +3° or -3° graphene orientation, whereas others are bi-crystalline, in which the crystal lattice of one half of the ribbon is rotated by $2\times3^\circ=6^\circ$ with respect to the other half. This data indicates that the nanoribbons nucleate in their center and then grow in opposite directions along their length.

Ultra-high vacuum STM, in collaboration with the group of Nathan Guisinger at Argonne National Laboratory, has been used to substantiate the LEED data and to determine the atomic nature of the graphene nanoribbon edges on Ge(001). Using topographic data alone, we can set

an upper limit on the edge roughness. For example, the representative 40 nm ribbon segment in Fig. 1 has roughness of < 0.5 nm (two lattice constants of graphene). However, we can learn more about the edge structure from quantum interference patterns caused by inter-valley backscattering (not shown) of charge carriers at the ribbon edges. The presence of coherent interference patterns at edges combined with the small line edge roughness indicates that the edges consist primarily of smooth armchair segments.

Interestingly, the Ge surface selectively forms hill-and-valley structures below the nanoribbons and below continuous graphene films (not shown). The facet angle is shallow for thin ribbons and becomes steeper, as the ribbons grow wider and eventually merge to form a continuous graphene film, with an angle of about 8°, consistent with the Ge(107) facet.

This breakthrough is important because the synthesis of nanoribbons with armchair edges, the definition of ribbons with width < 10 nm, and the direct integration of nanoribbons onto insulating or semiconducting platforms have been difficult. Our direct, self-defining growth offers precise control over the ribbon structure beyond the fidelity of top-down lithography and yields a relatively pristine nanoribbon/substrate interface. The ribbons are self-aligning, and ribbons with w < 10 nm can still be hundreds of nanometers in length, opening the door for exploration of dense nanoribbon arrays as logic, photonic, and sensing components in integrated circuits. Improved control over the ribbon placement will enhance the viability of these applications. These results are also technologically important because they enable a scalable, high throughput pathway for integrating nanoribbons directly on conventional semiconductor wafer platforms that are compatible with planar processing, like Ge wafers and potentially epitaxial Ge films on Si or GaAs wafers.

2. <u>Catalytic zigzag nanoribbon edge repair</u>

We have pioneered a method to repair the disordered edges of graphene nanostructures (that have been lithographically patterned from the top-down) and convert them into relatively smooth zigzag edges via annealing on a Cu substrate.

Overview: Top-down subtractive lithography has previously been used to pattern graphene nanostructures which lack ideal properties due to (i) limited resolution and (ii) disordered edges. We have invented a method to convert such disordered edges into relatively smooth zigzag edges via annealing on a Cu substrate at ~950 °C (Fig. 3).[2] The Cu catalyzes the re-arrangement of graphene edge atoms to energetically favorable sites, inducing zigzag edge faceting. We exploit processes that are inherent to graphene CVD on Cu substrates to drive the edge repair, in particular, the fact that both growing and etching graphene domains show preference to the zigzag edge due to favorable energetics or kinetics.

Some of the foundations for achieving this nanoribbon edge repair have already been presented during previous Synthesis and Processing meetings. We first demonstrated proof of principle catalytic edge repair for graphene nanoribbons patterned on the surface of Cu foils. However, due to the polycrystalline nature of the foils, the process was not robust or repeatable and thus it was difficult to conduct a comprehensive study of the phenomenon.



Fig. 3. Catalytic edge repair. Schematic (top) and SEM (bottom) of GNRs (A,B) after top-down patterning, and (C,D) after edge-annealing (SEM same magnification, scale bar = 100 nm). (E) Raman defect ratio I(D)/I(G) vs. (nanoribbon width)⁻¹ for edge-annealed (blue) versus top-down patterned (red) graphene nanostructures. (F) Line edge roughness before and after annealing.[2]

Since then, we have demonstrated improved repeatability by conducting the experiments on Cu(111) thin films on sapphire rather than foils. Moreover, we have advanced our understanding of the etching and growth reaction mechanisms and intermediates during graphene CVD and during catalytic edge repair during which growth and etching reactions are balanced.[3] We have now combined these advances and conducted a complete study of nanoribbon edge repair.

In our complete study[2], we have shown that the dimensions of graphene nanostructures can be increased, decreased, or held constant (Fig. 3A-D) during annealing by tuning the relative balance between growth and etching, described by a fundamental growth rate equation. To demonstrate the flexibility of the method, we lithographically patterned graphene nanoribbons with zigzag or armchair orientations, or alternatively perforated graphene with circular holes, and then annealed these nanostructures to realize zigzag edge termination in each case, with nanostructure feature size tailored from 8 to 80 nm. The annealed nanostructures have smoother zigzag edges (~40% reduction in 1σ line edge roughness, Fig. 3E), and Raman spectroscopy confirms that they have lower edge disorder than top-down patterned samples (Fig. 3F). We expect these results, combined with next generation state-of-the-art lithography, will enable the wafer scale patterning of narrow graphene nanostructures with smooth zigzag edges, suitable for many applications.

Future Plans

We will focus on fundamental studies of the nucleation and growth of graphene and graphene nanoribbons on Ge. The goal will be to fundamentally understand the synthesis so that we can better control it.

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Studies of Surface Reaction and Nucleation Mechanisms in Atomic Layer Deposition

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Program Scope

The overarching goal of this program is to understand the fundamental mechanisms of nucleation and growth in atomic layer deposition (ALD). ALD, a method for depositing thin films of numerous semiconducting, insulating and metallic materials using an alternating series of selflimiting reactions between gas phase precursors and the substrate, is proving to be an enabling technique for creating the innovative nanostructured materials needed for future applications, including those in solar energy and photoelectrocatalysis. Despite its growing technological importance, a fundamental, molecular-level understanding of most ALD processes is still lacking.

This project applies both experimental and theoretical methods to uncover surface reaction and nucleation mechanisms active during ALD. A combination of *in situ*, *in vacuo*, and *ex situ* X-ray photoelectron spectroscopy, infrared spectroscopy, synchrotron radiation photoelectron spectroscopy, and synchrotron radiation X-ray diffraction (XRD) and X-ray scattering studies are employed, together with complementary theory and modeling. We provide new mechanistic insights in representative ALD systems: those of metals (e.g. Pt, Ru) as well as those of binary and ternary metal oxides. The work aims to provide the scientific foundation required for the ultimate design and synthesis of new materials for applications in energy, electronics, and catalysis.

Recent Progress

Our results over the past two years have introduced several new insights into the mechanisms of nucleation and growth in both metal and metal oxide ALD, as described below. We also completed the construction of various instruments for performing *in situ* measurements (XRD, X-ray scattering, XPS, and IR) and have expanded our toolbox of *ex situ* techniques and analyses of ALD processes as well.

Understanding and Controlling Metal Nucleation by ALD

Over the past year, we continued fundamental studies aimed at understanding the processes of nucleation and growth during metal ALD. Our work explored several directions: nucleation of Pt on graphene substrates, the effect of more reactive counter-reactants on Pt ALD, and the nature of epitaxial Pt deposition on single crystal $SrTiO_3$.

Expanding upon our earlier studies of Pt ALD on highly ordered pyrolitic graphite (HOPG), we investigated the role of the substrate on Pt nucleation by studying ALD on graphene. We demonstrated the selective deposition of metal at the line defects of graphene, notably grain boundaries, by ALD, as confirmed by electron microscopy (Figure 1).



Figure 1. Selective Pt growth by ALD on one-dimensional defect sites of polycrystalline CVD graphene. (a) Schematic; (b) and (c) SEM images of CVD graphene on a glass substrate after 500 ALD cycles and 1000 ALD cycles of Pt deposition, respectively.

Figure 2. Apparent coverage measured by SEM versus substrate temperature of 400 cycles of Pt ALD using three counter reactants. ALD with O_3 can occur at temperatures as low as $100^{\circ}C$.

We showed that Pt is deposited predominantly on graphene's grain boundaries, folds and cracks due to the enhanced chemical reactivity of these line defects. The Pt-decorated graphene samples were then tested for hydrogen gas sensing at room temperature, in collaboration with the group of Prof. Zhenan Bao. The results show that selective functionalization of graphene defect sites, together with the nanowire morphology of the deposited Pt, yields improvements in sensing applications.

To understand if nucleation difficulties could be mitigated by more reactive counter reactants, we probed the effect of ozone on nucleation and growth during Pt ALD. Looking first at growth on SiO_2 , we showed that O_3 leads to a higher growth rate than that using either air or O_2 counter reactants, and also enables ALD at lower deposition temperatures (as low as 100 °C, see Figure 2). Interestingly, Pt ALD using air on an O_3 -pretreated surface showed almost the same growth rate as Pt ALD using O_3 . The data indicate that O_3 strongly affects the surface species toward fast nucleation of Pt.

We also showed that ozone has a strong effect on Pt nucleation on graphite. As we have reported previously, ALD Pt using O_2 is selectively deposited on the intrinsic step edges because the step edge sites are much more active for Pt nucleation than the basal planes. In contrast to O_2 , a continuous Pt film is obtained on the HOPG surface when O_3 is used (Figure 3). Pretreatment of the graphite by O_3 prior to Pt ALD using an O_2 reactant shows a similar, continuous Pt film morphology to that obtained from the full O_3 -based ALD process. Our analysis revealed that O_3 etches the graphite surface and generates pits containing additional step edges, resulting in an increase of Pt nucleation. The nucleation of Pt is less active at lower deposition temperatures because the generation of additional step edges is dependent on temperature. This Pt ALD process using a reactive O_3 reactant can be an effective route to fabricate uniform and continuous Pt films on 3D carbon substrates.



Figure 3. SEM images following 400 cycles of Pt ALD on graphite using O_2 compared with that using O_3 .

We also examined the epitaxial growth of Pt deposited by atomic layer deposition on crystal SrTiO₃ substrates, single as characterized using 2D grazing incidence xray diffraction (GIXRD) at SSRL. The orientation of the Pt thin film was determined by combining a series of GIXRD images to generate a Pt(111) pole figure. For SrTiO₃ [001] substrates, epitaxial growth was observed along with randomly oriented growth. For SrTiO₃ [101] substrates.

epitaxial growth and Pt [111] oriented fiber texture were observed. Six peaks within the Pt [111] fiber texture ring are present indicating preferential alignment with the substrate to minimize the energy at the Pt / $SrTiO_3$ interface.

Mechanistic Studies of Ternary Metal Oxide ALD

With the rapid expansion of potential applications of ALD materials, there is increasing interest in ALD processes that go beyond the deposition of binary materials to allow for the synthesis of alloyed, doped, ternary, or quaternary materials. However, for ALD of such materials, typically achieved by combining multiple binary ALD processes, it is often difficult to correlate the material properties and growth characteristics with the process parameters due to a limited understanding of the underlying surface chemistry.

We investigated growth of zinc tin oxide (ZTO) as a model system for ALD of ternary materials. ZTO films were deposited by alternating growth of tin oxide (SnO_x) and zinc oxide (ZnO) with tetrakis(dimethylamino)tin and diethylzinc precursors and water counter reactant. We showed that the growth rate of ZTO is strongly reduced as compared to the growth rates of the binaries. especially at low bilayer periods and low tin cycle fractions. By combining DFT calculations and in situ quadrupole mass spectrometry (QMS), we showed that the ZnO growth rate is reduced when SnO_x layers are inserted, with a significant reduction in surface reaction site density during even a single SnO_x cycle. DFT results suggest one possible explanation for the decrease in growth rate: it may be a consequence of the four exchangeable ligands of the TDMASn precursor used in SnO_x growth compared to the two ligands of the DEZn precursor used in the ZnO cycles. Another possible explanation is ligand poisoning. By gas-phase Fourier transform infrared (FTIR) spectroscopy, the dimethylamine product of the SnO_x ALD process is observed not only during SnO_x ALD but also when depositing ZnO after SnO_x, indicating incomplete removal of the ligands of the tin precursor from the surface. These remaining ligands may poison the surface against further reaction, and thereby contribute to the observed nucleation delay for ZnO ALD during the deposition of ZTO. The correlation between precursor molecular structure and materials growth that we established for the ZTO system will likely apply to other ALD processes where precursors follow ligand-exchange surface chemistries as well.

Another important question in ternary metal oxide ALD is how well mixed the constituents are in the film. The extremely surface sensitive technique of low energy ion scattering (LEIS) was applied to the ZTO ALD model system to address this question. At the low temperatures used for deposition (150°C) there is little evidence for atomic scale mixing even with the smallest possible bilayer period, and instead a morphology with small ZnO inclusions in a SnO_x matrix is deduced. Post-annealing of such laminates above 400 °C however produces a stable surface phase, likely the inverted spinel of zinc stannate, Zn_2SnO_4 , with a 30% increased density. Further annealing to 800 °C results in films containing crystalline Zn_2SnO_4 , or multilayered films of crystalline ZnO, Zn_2SnO₄ and SnO₂ phases, depending on the bilayer period.



Figure 4. Instantaneous growth rates extracted from ellipsometry. Steady state binary growth rates indicated by dashed horizontal lines.



Figure 5. Illustration of suggested island type growth mode of ZnO on SnO_x , and layer-by-layer type growth of SnO_x on ZnO.

The instantaneous growth rates of ZnO on SnO_x and SnO_x on ZnO were measured as a function of number of cycles past the interface. Mechanistically, the behavior in Figure 4 may be understood as a consequence of a limited number of nucleation sites found on the SnO_x surface, which initially suppresses the growth rate of the ZnO.

Eventually the surface area of the growing ZnO islands surpasses that of a corresponding planar growth surface, temporarily leading to a higher growth rate compared to steady state. As the islands coalesce into a film after additional interlayer cycles, the steady state growth rate will be approached. The latter is illustrated by the drawn, dotted part of the curve in Figure 4. Interestingly, the initial SnO_x growth exceeds the steady state growth rate observed for thicker films. We conclude that ZnO initially nucleates more slowly by island type growth on SnO_x than on ZnO, and conversely that SnO_x grows faster on ZnO than on SnO_x by layer-by-layer type growth (see illustration in Figure 5), due to varying densities of hydroxylated surface sites available on these surfaces and surface poisoning by persisting tin precursor ligands.

Future Plans

We will seek a deeper understanding of ALD mechanisms in metal, metal oxide, and metal sulfide systems. We plan to extend our studies of ALD on different substrates, including those of 2D materials such as MoS_2 or WS_2 . The results from these studies are intended to help us to discover strategies for enhancing the nucleation of ALD on technologically-important surfaces for production of uniform ultra-thin films, which remains a key challenge in the field. We will also continue to build our program on mechanistic studies of alloyed, doped, ternary, and quaternary metal oxide ALD, which have many interesting materials properties as well as many unanswered questions as to their nucleation, growth and degree of intermixing. We will also explore a new research direction: the synthesis of 2D materials via ALD. 2D materials such as MoS_2 are currently of great interest due to their important electronic properties as well as catalytic activity, and synthesizing thin film coatings of these 2D materials opens many interesting possibilities. However, there is almost nothing known about the mechanism of film formation, and we will perform studies to elucidate the steps by which both in-basal-plane and out-of-plane bonds form and propagate.

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Molecule–Sorbent Interactions in Metal Organic Framework Materials

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Program Scope

The aim of this program is to develop a fundamental understanding of the interaction of guest molecules such as H₂, CO₂, N₂, and CH₄ in porous metal organic framework (MOF) materials, using a combination of novel synthesis, *ab initio* modeling, and characterization. In particular, we combine high-pressure/low-temperature *in-situ* infrared (IR) absorption and Raman measurements with gas adsorption-desorption experiments and calculations based on density functional theory, to study molecular interactions in different MOF materials. One of the goals is to provide insight concerning the role of unsaturated metal centers in enhancing molecular uptake, selective adsorption, and diffusion. The short-term impact of the proposed work is the control and understanding of common MOF systems, making it possible to determine the theoretical loading limits and stability of a specific class of materials. The long-term impacts are the development of 1) theoretical and experimental methods to gain a fundamental understanding of molecular interactions within MOFs, and 2) new guidelines to synthesize microporous MOFs with tailored molecular binding, selectivity, and other targeted functionalities.

Recent Progress

a) Structural, elastic, thermal, and electronic responses of small-molecule-loaded metal-organic framework materials [1] -We have combined infrared spectroscopy, nano-indentation measurements, and *ab initio* simulations to study the evolution of structural, elastic, thermal, and electronic responses of the metal organic framework MOF-74-Zn when loaded with H₂, CO₂, CH₄, and H₂O. We find that the molecular adsorption in this MOF triggers remarkable responses in all of these properties of the host material, with specific signatures for each of the guest molecules. With this comprehensive study we are able to clarify and correlate the underlying mechanisms regulating these responses with changes of the physical and chemical environment. Our findings suggest that metal organic framework materials in general, and MOF-74-Zn in particular, can be very promising materials for novel transducers and sensor



Figure 1. Cover page of J. Mater. Chem. A, featuring our study.

applications, including highly selective small-molecule detection in gas mixtures. This work was featured on the cover page of J. Mater. Chem. A – see Figure 1.

b) Water reaction mechanism in metal organic frameworks with coordinatively unsaturated metal ions: MOF-74 [2,3] – Water dissociation represents one of the most important reactions in catalysis. However, its mechanism on most oxide surfaces is not well understood due to the experimental challenges of preparing surface structures and characterizing reaction pathways. We proposed the metal organic framework MOF-74 as an ideal model system to study water reactions. Combining *in situ* IR spectroscopy and *ab initio* calculations, we explored the MOF-

74/water interaction as a function of vapor pressure and temperature. We showed that, while adsorption is reversible below the water condensation pressure at room temperature, a reaction takes place at ~150 °C even at low water vapor pressures. This important finding is unambiguously demonstrated by a sharp absorption band that appears at 970 cm⁻¹ when D₂O is introduced above 150 °C, which we attribute to an O–D bending vibration on the phenolate linker



using D_2O , but it becomes obscured when using H_2O .

(see **Error! Reference source not found.**). Although H₂O undergoes a similar dissociation reaction, the corresponding O–H mode is too strongly coupled to MOF vibrations to detect. *Ab initio* calculations could identify the O–D mode at 970 cm⁻¹ and derived a pathway and kinetic barrier for the reaction: the D (H) atom is transferred to the oxygen of the linker phenolate group, producing the notable O–D absorption band at 970 cm⁻¹, while the OD (or OH) binds to the open metal sites. This novel mechanism for water dissociation adds to the understanding of molecular water interaction with cation-exposed surfaces to enable development of more efficient catalysts for water dissociation.

c) Competitive co-adsorption of CO_2 with H_2O , NH_3 , SO_2 , NO, NO_2 , N_2 , O_2 , and CH_4 in M-MOF-74 (M = Mg, Co, Ni): the role of hydrogen bonding [4] – By examining the competitive coadsorption of several small molecules in M-MOF-74 (M= Mg, Co, Ni) with in-situ infrared spectroscopy and *ab initio* simulations, we find that the binding energy at the most favorable (metal) site is not a sufficient indicator for prediction of molecular adsorption and stability in MOFs. Instead, the occupation of the open metal sites is governed by kinetics, whereby the interaction of the guest molecules with the MOF organic linkers controls the reaction barrier for molecular exchange. Specifically, the displacement of CO₂ adsorbed at the metal center by other molecules such as H₂O, NH₃, SO₂, NO, NO₂, N₂, O₂, and CH₄ is mainly observed for H₂O and NH₃, even though SO₂, NO, and NO₂, have higher binding energies than CO₂ and H₂O. Ab initio simulations evaluated the barriers for the $H_2O \rightarrow CO_2$ and $SO_2 \rightarrow CO_2$ exchange to be 13 and 20 kJ/mol, respectively, explaining the slow exchange of CO₂ by SO₂, compared to water. Furthermore, the calculations revealed that the kinetic barrier for this exchange is determined by the specifics of the interaction of the second guest molecule (e.g., H_2O or SO_2) with the MOF ligands. Similar considerations apply to the other molecules, accounting for much easier CO_2 exchange with NH₃ than with NO, NO₂, CH₄, O₂, and N₂ molecules. In this work, critical parameters such as kinetic barrier and exchange pathway were unveiled and provided insight into the mechanism of competitive co-adsorption, underscoring the need of combined studies to uncover the atomistic interactions influencing co-adsorption of small molecules in MOFs.

d) The first case of commensurate adsorption of atomic gas in a microporous MOF which exhibits the highest selectivity of xenon over other noble gases [5] – In industry, cryogenic rectification for separating xenon from other noble gases such as krypton and argon is an energy and capital intensive process. We showed that a microporous metal-organic framework (MOF), namely $Co_3(HCOO)_6$ is capable of effective capture and separation of xenon from other noble

gases. Henry's constant, isosteric heats of adsorption (Q_{st}), and IAST selectivity were calculated based on single component sorption isotherms. With the highest Q_{st} reported to date, Co₃(HCOO)₆ demonstrates high adsorption capacity for xenon and highest IAST selectivity for Xe-Kr among all MOFs investigated so far. To mimic real world conditions, breakthrough experiments were conducted on Xe-Kr binary mixtures at room temperature and 1 atmosphere. The results were consistent with the calculated data. Our gas adsorption measurements and molecular simulation study also revealed that xenon could be adsorbed, representing the first example of commensurate adsorption of atomic gases near ambient conditions.

e) Distinct reversible colorimetric and fluorescent low pH response on a water-stable zirconium-porphyrin metal-organic framework [6] - We synthesized a water-stable zirconiumporphyrin MOF (PCN-222) and investigated its reversible colorimetric and fluorescent "turn-off-turn-on" pH response. The tcpp ligand in the mesoporous framework is the main reason for the very sensitive optical signal. The colorimetric response was achieved under acidic conditions starting at pH = -3 and persisted under concentrated acidic conditions. The sensitive optical response properties of the soluble porphryin-derivative molecular species could be realized in an easily accessible and stable, solidstate single-phase bulk material and without the formation of aggregates. Additionally, we showed that the material has the advantage of full reversibility and reusability that outperforms its molecular analogues and is highly suitable to act as both a



luminescent as well as colorimetric solid-state sensor for the low pH values covering a relatively wide pH range. To the best of our knowledge, this is the first report of a colorimetric MOF pH sensor. This work was featured on the front cover of Chem. Comm.

f) *Porous luminescent MOFs for explosive sensing* [7,8] We designed. synthesized. and structurally characterized a group of luminescent metal-organic frameworks (LMOFs) with closely related structures. Engineering one of the ligand with different functional groups led to distinct porosity and luminescent properties of these compounds, which drastically affected their sensing performances. The effective detection of high explosive RDX with extremely low vapor pressure was achieved by an indirect route via fast and highly sensitive sensing of a ketone vapor that inevitably co-exists in the explosive product. IR spectroscopic and guest sorption studies show that LMOF-121 interacts more strongly with acetone than with cyclic ketones as a result of size



compatibility. On the other hand, LMOF-202 adsorbs other ketones more strongly than LMOF-121. The effects of electron and energy transfer processes on both fluorescence enhancement (by ketones) and quenching (by DNT) were elucidated for LMOF-202, by comparing to LMOF-121 with similar porosity but different electronic structure. Tuning the porosity and electronic properties specifically towards a detection target could significantly improve sensitivity and selectivity. Such a strategy can be very helpful in designing highly efficient sensory materials.

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Future Plans

Our studies have shown that there are three fundamental roadblocks to the development of MOFs for novel applications: synthesis methods, ability to incorporate species post processing (mass transport), and charge transfer mechanisms between host and guest; we plan to tackle all three issues. For synthesis, we will focus on a systematic approach using pre-formed metal precursors (clusters) and tailored ligands with targeted functionalities instead of using simple metal salts. This novel approach will be supported by *ab initio* calculations and spectroscopic studies to provide direct guidance on synthesis optimization. Second, we will explore the diffusion of a variety of species in MOFs, from small gas phase molecules to ions in solution. This will involve ab initio molecular dynamics simulations and transition-state searches, which will identify the "bottlenecks" to diffusion and thus provide guidelines for the synthesis of novel MOFs with better diffusion properties. Furthermore, we will carry out an in-depth study to investigate the effect of guest molecules on MOFs via changes in optical behavior such as luminescence signal changes. We also plan to incorporate catalytic activity by incorporating molecular catalysts within the MOF, guided in the best choices for active metal and ligands by *ab initio* simulations. Finally, we will examine the interaction of molecular species with the MOF host to understand the mechanism of charge transfer from or into the framework. These phenomena have a strong impact on properties such as luminescence, photo-reactions, and photocatalysis.

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A unified understanding of residual stress in thin films: kinetic model and experiments

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Program Scope

Controlling residual stress is critical for enhancing performance and reliability in thin films. Yet despite much study, the connection between the film growth process and the resulting stress is not well understood. The goal of the work in this program is to develop a comprehensive framework that can quantitatively explain and predict the residual stress in terms of the underlying kinetic processes and microstructural parameters.

Wafer curvature is used to measure the stress evolution in real time for different processing conditions and microstructure. To interpret these data, we have developed a model that relates the stress to the underlying physical processes. In this abstract we report on advances in several different topical areas: 1) the use of patterned films to understand stress vs. thickness; 2) the competing effects of grain growth and growth rate on stress evolution and 3) extension of the model to interpret measurements of sputter-deposited films.

Recent progress

Model for stress: The work is centered around a model we have developed that predicts the stress evolution during thin film growth (described more fully in [1]). The model focuses on the stress-generating processes that occur at the top of the grain boundary as the film grows (i.e., at the triple junction shown schematically in figure 1). Tensile stress (σ_{T}) is generated by the attractive force between adjacent grains as they merge to form new segments of grain boundary [2]. Compressive stress (σ_{C}) is generated by the insertion of atoms into the grain boundary, driven by the non-equilibrium growth conditions that raise the chemical potential on the surface. Balancing these kinetic processes produces a rate equation for the stress in each layer (indexed by *i*) as the film grows:



junction Figure 1. Schematic of film around triple junction for model of stress evolution.

$$\sigma_{i} = \sigma_{c} + (\sigma_{T} - \sigma_{c}) \cdot \exp \frac{-\beta D}{L \frac{dh_{gb}}{dt}}$$
(1)

where *D* is an effective diffusivity, *L* is the grain size and β is a kinetic parameter. The rate at which the grain boundary grows (dh_{gb}/dt) determines the relative balance between the stress-generating processes.

Understanding stress vs thickness by using patterned films: In many films, the stress

changes from tensile to compressive as the thickness increases, which has been a long-standing puzzle. We can explain this with our growth model by considering how dh_{gb}/dt changes as the microstructure evolves during growth. At the initial point of coalescence, the grain boundary grows very rapidly because of the steep contact angle between the coalescing grains. As the film becomes thicker, however, the velocity of the grain boundary decreases asymptotically to the average rate (*R*). The dependence of eq. 1 on dh_{gb}/dt shows how this makes the stress less tensile/more compressive with increasing thickness.

Although this explains why the stress changes, it is difficult to compare quantitatively with typical experiments where the grain shape is not known. To address this, we have grown films on lithographically-patterned substrates so that we can control the film morphology. We use electrodeposition so that the



Figure 2. SEM image of Ni islands in a) 2-d and b) 1-d arrays.

islands grow with a constant radial growth rate. For a 2-d array, the islands grow in the form of hemispheres while for a 1-d array they grow in the form of half-cylinders. SEM images of each type of surface morphology are shown in figure 2.

These morphologies allow us to calculate the stress-thickness evolution for comparison with the experiments. For the 2-d patterned films, we have shown that the model agrees with the data for multiple growth rates using the same model parameters [3]. More recently we have measured the stress evolution in 1-d arrays with different spacings [4]. Measurements of the stress-thickness for a 1-d pattern spacing of 5.3 μ m are shown in figure 3 for multiple growth rates from 0.32 - 5.27 nm/s. The calculations from the model (solid lines) agree very well with the data, capturing the dependence on the growth rate. All the calculations shown in the figure were done with a single set of values for the model parameters ($\sigma_T \sigma_C$ and βD); the only difference between them is the growth rate.

To understand the dependence on the length scale, similar measurements were done on patterned films with different spacings, *L*. The data for were fit to the model using the same values of σ_C and βD but allowing σ_T to be different for each spacing (based on the Hoffman model [2]). A plot of the steady-state stress vs. growth rate for each value of *L* is shown in figure 3b (the solid line is the fit to the model). The values of the parameter σ_T from the fitting agree with $L^{-1/2}$ as predicted by the model.



Figure 3. a) Stress-thickness vs. time for 1-d island array with spacing of 5.3 μ m. b) Steady-state stress for 1-d arrays with different spacings. Solid lines are fit to model.

Dependence of steady-state stress on growth rate and grain size: In earlier work, we have shown that the dependence of the steady-state stress on the growth rate in electrodeposited Ni is well-explained by the model. However, in many films that grain



Figure 4. a) Measurements of stress-thickness vs thickness at different growth rates (shown by yellow lines) for electrodeposited Cu. b) FIB cross-section used to determine grain size at different thicknesses. c) Stress vs. growth rate and grain size.

size changes as the thickness increases which can modify the stress. If the grain size changes throughout the thickness of the film (referred to as zone II growth [5]), this can lead to an additional stress due to densification of the film. In other systems, the grain size changes primarily at the surface (zone T) or not at all (zone I).

Our recent studies have focused on understanding the combined effects of grain size and growth rate on the stress evolution. In the first series of experiments, we have studied electrodeposited Cu that grows with a zone T microstructure. Measurements were performed at different growth rates as shown in figure 4a. After growth, the film was cross-sectioned in order to determine the grain size corresponding to each period of growth at different rates (figure 4b). From these measurements we are able to plot the simultaneous dependence of the steady-state stress on the growth rate and grain size. For comparison with the model, we calculate the stress over this range of parameters using eq. 1 and setting dh_{gb}/dt equal to the average growth rate (appropriate for the steady-state regime). The colored surface corresponds to the calculated values from the model using only 3 parameters to fit the entire set of data. The shape of the surface shows the simultaneous growth rate and grain size dependence of the steady-state predicted by the model, consistent with the measurements.

More recently, we have extended this to include films that grow in zone II through a collaboration with Prof. Carl Thompson at MIT. Measurements by Yu and Thompson [6] show that the stress during UHV evaporation of Ni films does not reach a steady-state because of grain growth in the film. Importantly, they also measured the grain size as a function of thickness and show that it depends linearly on the thickness. We have performed preliminary analysis of these data in which we include the tensile stress due to grain growth in the film. We have found that the grain size dependence in our model coupled with tensile stress due to grain growth is able to explain the measured stress evolution as a function of temperature and growth rate.

Extension of model to include effects of energetic particles (sputter deposition): Recent measurements by Abadias' group [7] have quantified the stress during sputter deposition of Mo films at different growth rates and pressures (shown in figure 5). The effect of the energetic particles leads to different behavior (i.e., more compressive/less tensile stress with higher growth rates) than for non-energetic growth. We extended our model to include effects of energetic particles at the grain boundaries and in the bulk of the film.

Preliminary results suggest that the model (shown by solid lines) is able to explain both the growth rate and pressure dependence. It also explained measurements of stress vs. grain size (not shown).

Future Plans

In the future we will continue efforts to validate and improve the model in order to build a comprehensive understanding of stress in thin films. The results will hopefully establish this model as a paradigm for understanding residual stress that can be used to predict stress under different conditions and guide optimization of growth parameters.



Figure 5. Measurements of steadystate stress vs. growth rate and pressure for Mo deposited by sputtering.

Experiments will be performed in a number of materials and deposition systems (evaporation, electrodeposition, sputter deposition, ion-assisted growth) to develop a common framework that can include all the different effects of the processing conditions. Analysis of this experimental work will enable us to build up a database of parameters for different materials that can be compared with other experiments to explore their physical basis. For instance, measurements of stress at different temperatures will let us determine the activation energy for the diffusivity that can be compared with other studies of grain boundary and surface diffusion. Similarly, the tensile stress parameters can be compared with surface/interfacial energies for validation of the Hoffman model. We will also perform a systematic study of adding energetic effects to growth effects by measuring the same material (e.g., Cu) during evaporation, evaporation with ion bombardment (ion-assisted growth) and sputter deposition. Modeling efforts (e.g., molecular dynamics (MD), finite element analysis, kinetic Monte Carlo (KMC), etc.) will be done in collaboration with others to test the mechanisms included in the model.

In the longer term, we plan to extend the model to study the growth of alloys. The equations for the stress will be modified to include the effects of two mobile species. Preliminary studies suggest that the results will be similar in form to eq. 1 but with more complex parameters depending on the different species. This suggests interesting possibilities such as the introduction of a small concentration of a highly mobile species to enhance compressive stress in the film. An experimental program to study stress in alloy films will guide the model development and test the results.

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Electric-Loading Enhanced Kinetics in Oxide Ceramics: Pore Migration, Sintering and Grain Growth

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Program Scope

Understanding the thermodynamics and kinetics of new microstructure-relevant phenomena triggered or assisted by electric loading in oxide ceramics, especially those of zirconia and structurally related oxide.

Recent Progress

Electric field has significant effects on microstructure evolution (e.g. sintering, grain growth, etc.) of ceramics due to Joule heating, off-diagonal coupling of kinetics and non-equilibrium defect chemistry. Recent progresses from this project include:

I. Under constant environment heating rate and applied voltage, an electric field must lead to thermal runaway in any materials with a negative temperature coefficient of resistivity [1] and, for partially dense ceramics, flash sintering. We have obtained an analytic solution to the thermal runaway problem [2-3], which correctly predicts the runaway temperatures in excellent agreement with the on-set temperatures of more than a dozen flash-sintering studies. The analysis revealed a strong correlation with the resistivity class of the material, thus adding to its predictive power.

II. In fast-ion conductors which includes fast-ion wind and slow counter-ion diffusion, their coupling via short-circuit paths can be made possible by an electric field/current [4]. Such coupling can then completely destabilize the otherwise extraordinarily stable microstructure of these ceramics at unexpectedly low temperatures. Examples so far observed in zirconia include migration of pores (hence sintering) [4-6], gas bubbles [5-6], and space-filling particles (e.g., alumina and silica.) Other couplings of the above kind may conceivably exist in other material classes, thus causing their microstructure instability.

III. In kinetics-limited cases, an electric field may exacerbate the mismatch between a large energy flux and slow interface kinetics, creating non-equilibrium conditions allowing huge defect supersaturation. For example, in zirconia (both 8YSZ in the cubic form and 3YSZ in the tetragonal form) there is now reliable experimental [7] and theoretical evidence that reduced cations rendered by an electric field/current/potential enjoy much faster kinetics. In this way, sintering and grain growth are locally enhanced as an indirect result of electric field.

IV. Since the electric field/current imposed in experiments is often very large, ample opportunities exist for Rayleigh-type instabilities to arise leading to localization of

field/current/energy. Examples of this kind have been seen in 3YSZ, leading to dendrite-like grains with a huge (~100) aspect ratio.

Future Plans

We will collect detailed statistics of particle migration and dendrite-like grains to allow microstructure modeling. Bicrystal experiments on pore and particle migration will be conducted to isolate the effect of grain boundaries and crystallography. Defect calculations based on empirical potentials and first-principles will be performed to understand the kinetics under equilibrium and supersaturated conditions. Experiments under conditions that simulate electrically-induced supersaturation will be designed to provide additional tests of these ideas.

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Novel sample structures and probing techniques of exotic states in the second Landau level

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Program Scope

The two-dimensional electron gas hosts a wealth of unusual phases arising from the interplay of reduced dimensionality and strong electron-electron interactions. Recently it was suggested that this system may support unusual ground states which harbor exotic particles with special topological properties. Specifically, the ground states are thought to have Abelian and non-Abelian properties of various kinds [a]. The most interesting states form in the region of the phase space commonly referred to as the second Landau level.

Examples of such unusual ground states in the second Landau level are the fractional quantum Hall states at the quantum numbers 5/2 and 12/5. These ground states are not only of fundamental interest as they may manifest behavior not seen in any other physical system, but also may find technological utility in fault-tolerant schemes for quantum computation [b]. These exotic states are, however, fragile and hence they develop only under special conditions.

Two-dimensional electron gases are realized in a large variety of semiconductor hosts. GaAs/AlGaAs plays an important role among these semiconductors and the low temperature mean free path is the longest. Because of the very long mean free path, conditions are favorable for the development of a large number of exotic ground states, including several states believed to be non-Abelian.

At Purdue University we have developed a synergistic experimental program based on systematic growth and ultra-low temperature measurement of high quality GaAs/AlGaAs crystals tailored to answering outstanding questions concerning the collective behavior of the correlated electronic ground states of the two-dimensional electron gas. Our primary focus is the study of the fractional quantum Hall states and exotic electronic solids of the second Landau level, i.e. corresponding to Landau level filling factors $2 \le v \le 4$. The goal of our program is to use state-of-the-art growth and incisive experimental measurement techniques to generate new insight into the nature of the exotic correlated states of the second Landau level.

Recent Progress

This project builds on the ongoing collaboration of the PIs and unique experimental capabilities developed at Purdue University. **Manfra** operates state-of-the art MBE growth producing wafers with record high mobility. **Csathy** has an ultra-low temperature instrument capable of producing one of the lowest electron temperatures of 5 mK.

Advances in material growth In the past year we have made several advances in material quality and improved our understanding of the relationship between disorder-induced scattering, ever-present density inhomogeneity, and low temperature transport characteristics in the second Landau level. Improvements made to our MBE system and materials preparation techniques resulted in a dramatic improvement in low temperature mobility. We produced samples with

mobility in excess of $35 \times 10^6 \text{cm}^2/\text{Vs}$ - a 75% improvement over our first growth campaign. Importantly, we discovered that the purity of gallium source material is the primary limiting factor in the achievement of ultra-high mobility. As shown in the Fig. 1 below, in-situ purification of gallium resulted in discrete jumps in mobility.

While mobility is one metric of film quality we have also made progress in our understanding of what parameters control the strength of the fragile states in the second Landau level. In collaborative work with the Folk group at Univ. of British Columbia we demonstrated



Figure 1: Mobility as a function of growth number and outgassing of gallium source.

the careful study of low temperature illumination and thermal annealing can increase the excitation gap at v=5/2 ($\Delta_{5/2}$) to 0.6K [11]. While $\Delta_{5/2}$ increases by a factor of 3 in these illumination experiments. mobility changes minimally. indicating that the disorder that controls the strength of the gap is not the same that sets mobility. We have initiated experiments to determine what metrics of two-dimensional electron gas quality measured during sample screening at T=0.3K correlate best with low temperature (T=10mK) behavior in the second Landau level. In addition to mobility we also measure quantum scattering time and the

resistivity at v=5/2 at T=0.3K. We find interesting behavior where the resistivity at 5/2 saturates to a minimum value of approximately 40 Ω /sq. even as the mobility continues to improve during the growth campaign (see Fig. 2). Our initial data indicate that the value of 5/2 resistivity at T=0.3K correlates inversely with the strength of the v=5/2 gap and is a better indicator of transport in the second Landau level at low temperatures than mobility.

Studies of the effects of heterostructure design We have also studied the impact of heterostructure design on the transport properties in the second Landau level in samples with an in-situ back gate [2]. In this work we demonstrated the placement of AlAs/GaAs superlattice between the back gate and the 2DEG has enormous impact on reducing the gate-to-2DEG

leakage current. Reduction of gate leakage is extremely important in devices designed to explore states in the second Landau level. In this work we demonstrated that leakage current as low as a few 10s of picoamps can result in heating detrimental to observation of fragile correlated states in the second Landau level. Properly designed heterostructures allowed us to produce devices that could be tuned from full depletion up to an electron density of 3.35×10^{11} cm⁻², where we observed $\Delta_{5/2}$ =625mK, the highest value to be reported to date. These devices form a novel platform where the properties of the second Landau can be explored as a function of the electron density.



Figure 2: Resistivity at 5/2 filling at T=0.3K as a function of mobility.

Alloy disorder and the even denominator fractional states Unraveling the impact of disorder is an important endeavor in contemporary condensed matter physics. Disorder is well understood in the single particle regime, but remains under scrutiny in novel systems such as topological insulators and atomic condensates. In contrast, understanding disorder in correlated electron systems, often referred to as many-body localization, continues to pose serious challenges. The Molecular Beam Epitaxy technique allows not only the growth of very low disorder 2DEGs, but

also enables controlled introduction of minute amounts of disorder into the 2DEG. Such specially tailor samples with one kind of disorder, called alloy disorder, were recently grown by Manfra [4] and studied at low temperatures in Csathy's laboratory [3]. As reported in a recent Physical Review Letters, a very surprising lowering of the mobility threshold for the even denominator 5/2 fractional state has been observed. Indeed, in high quality samples the 5/2 state has not been observed below the mobility of $7x10^6 \text{cm}^2/\text{Vs}$. In contrast, Csathy and his students found a mobility threshold in alloy samples of only $1.8x10^6 \text{cm}^2/\text{Vs}$. The lowering of the mobility threshold is currently not yet understood. However, these results are expected to stin



Figure 3: The gap at 5/2 filling as a function of mobility for pristine and alloy samples.

understood. However, these results are expected to stimulate theoretical research on disorder effects and provide input for the design of future, improved sample structures.

Tuning the exotic states with hydrostatic pressure One current focus of Csathy's research is the development of novel, incisive techniques probing the two-dimensional electron gas. Historically the most popular measurement technique used in investigations of this system is electronic transport. However, over the last decade or so it became increasingly clear that the probing of the new topologically ordered states requires more sophisticated techniques. Measurement of these systems at high hydrostatic pressures is one such technique currently being implemented by Csathy. The commercial pressure cell used is seen in the figure in the right. At pressures of the order of 10,000 atmospheres one can tune many relevant quantities which are expected to impact numerous ground states. We have recently discovered a novel transition from a fractional quantum Hall state to an electronic stripe phase [1].



Figure 4: The application of hydrostatic pressure induces an unexpected phase transition.

Collaborative efforts Under this program, **Manfra** has grown high quality materials used by several researchers, many of whom are DOE supported: Piczuk at Columbia, Zudov at Univ. Minnesota, Kono at Rice, and Engel at the Nationa High Magnetic Field Lab in Tallahassee [5-13]. **Csathy** is using the ultra-low temperature capability in his lab to work with two other DOE supported colleagues: Du at Rice [14] and Rokhinson at Purdue.

Future Plans We will continue our effort in studying disorder effects by expanding the energy gap measurements for other types of well-controlled disorder, such as charged disorder. We expect that disorder-specific information will guide us in further improvements of the growth process and may lead to new insight of the behavior of these systems. Encouraged by our recent results, we will continue to study pressure effects in the GaAs system. Specifically, we will investigate the spin polarization effects in the exotic ground states. We have recently started an effort to study the evolution of the interesting ground state with the width of the quantum well they reside in. Such investigations involve a coordinated effort between growth and ultra-low temperature measurement and are part of our long term effort aimed at exploring unconventional collective behavior in low-dimensional systems.

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Emergent properties of complex transition metal compounds.

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Program Scope

LaCNS, a DOE EPSCoR program, aims to build a major neutron scattering infrastructure capable of treating both soft and hard materials. The objectives of this initiative include the discovery of the role of coupling of degrees of freedom that determine the emergent properties of complex materials, the training of students and postdocs in synthesis and neutron scattering techniques, and the building of new scientific communities who will become the next generation of neutron users with a specific target of increasing the base of users of the Spallation Neutron Source and the High Flux Isotope Reactor in the USA.

The main scientific focus of this program is to understand the role of coupling between the important degrees of freedom in complex materials and its impact on the structure/property relationship, and to explore how this information can be applied in the guided-design of materials with desired properties. For hard materials, our goal is to tune dominant couplings that impact the magnetic, electronic, and phonon properties of complex transition metal compounds to enhance a critical property in order to derive new functionality. Since neutron characterization often requires the availability of large high quality single crystals, a major thrust in this research program focuses on their synthesis. Students and postdocs are being trained in a variety of synthesis techniques, including, solid-state reactions, arc melting, chemical vapor transport, metallic flux growth, RF induction melting, Bridgman, Czochralski, high pressure/high temperature growth, and optical floating zone. In addition to supporting the mission of the LaCNS, our single crystal growth activities strengthen the United States' presence in the global synthesis community, which has weakened over the last few decades.

Recent Progress

The materials systems under investigation in the LaCNS hard matter program include transition metal oxides such as Sr_2RuO_4 (Sr214) and $Sr_3Ru_2O_7$ (Sr327) which have been of continuing interest because of the competing magnetic states and their connection to *p*-wave superconductivity. Here we focus on Ru-site substitutions which tend to modify the lattice and nucleate magnetically ordered phases. The evolution of the spin-lattice coupling with chemical substitution is investigated using various techniques including neutron scattering. The growth of large single crystals with high purity is essential. The floating-zone technique is ideal for ruthenates, since the process does not require a crucible and the starting materials are well mixed

in the liquid state. However, due to the high melting temperature and the volatile nature of Ru metal, the growth of either single-layered or double-layered ruthenates requires precise control over the starting composition, atmosphere, and growth rate. Recently we have discovered that Fe substitution for Ru in Sr214 leads to a commensurate antiferromagnetic (AFM) ordering which is distinct from Mn or Ti substitutions which lead to an incommensurate AFM state or from Co doping resulting in a ferromagnetic (FM) ground state¹. This magnetic order is accompanied by charge localization suggesting a strong coupling between the charge and magnetic degrees of freedom. Similarly, we have synthesized large single crystals of Sr₃(Ru_{1-x}Mn_x)₂O₇ for exploring charge-spin-lattice couplings. Mn doping tends to reduce the structural

distortion and at the same time enhances AFM interactions resulting in an unusual quasi-2D AFM order². Of particular interest is the non-standard temperature dependence of the AFM order parameter and the spin dynamics. Using neutron scattering, we find, for the first time in the Sr327 system, an energy gap for spin wave excitations for x=0.16 demonstrating a Mn induced anisotropy.



Despite the separation between CoO_4 tetrahedra in the lattice structure of Ba_2CoO_4 (Fig. 1), it is AFM below 25 K. Large single crystals have been grown using the floating-zone technique. With the application of an O_2

atmosphere during the growth, stoichiometric Ba_2CoO_4 can be obtained, implying that Co is in its highest oxidation state. Using neutron scattering, we identified a spin gap due to the singleion anisotropy of Co⁴⁺[3]. Moreover, there is clear dispersion along the *a*-axis but not along the *c*-axis, indicating low-dimensional magnetism.

We also have a strong synthesis effort in designing materials with unconventional but highly desirable properties. Currently, we are investigating several materials that are relatives to the Febased superconducting systems. Using the flux method, we have successfully grown single crystals of Cu_xFeAs, which is isostructural (Fig. 2) to superconducting LiFeAs⁴. Here we find that uniaxial pressure does not induce magnetic correlations as expected. Although Cu_xFeAs is isostructural to LiFeAs (Fig. 3)⁴, it is not superconducting. Instead our neutron scattering experiments revealed a collinear G-type AFM order below 220 K. This state evolves into a canted AFM state below 142 K explaining the weak FM behavior observed below 60 K. The G-



type AFM order of Cu_x FeAs bears striking similarity to the high- T_c cuprates, thus directly bridging the Fe-based and Cubased unconventional super-conducting systems. Other related materials that we are exploring include newly discovered BaMn₂Sb₂ which is isostructural to BaFe₂As₂, a member of the 122 family of superconductors⁵. Large single crystals of BaFe₂As₂ and Ba(Mn_{1-x}Fe_x)₂Sb₂ were grown to explore the magnetic, charge carrier, thermodynamic, and structural properties. Recently, Liu et al. have synthesized a new topological semimetal, Sr_{1-x}MnSb₂ that is likely the first FM Weyl semimetal⁶. The Weyl semimetal state refers to a Dirac semimetal that lacks either time-reversal or space inversion symmetry so that each Dirac point with chiral symmetry splits into two Weyl points. Here we have characterized the magnetic ordering of this interesting system finding two magnetically ordered structures at high and low temperatures (Fig. 3).

Using Bridgman and optical floating zone techniques, we have synthesized large single crystals of $Fe_3Ga_4[7]$. Our neutron scattering data indicate that an incommensurate spin density wave (SDW) ordering competes with a FM ground state such that there is a reentrance of the FM state above 300 K. In addition, we have explored the sensitivity of the SDW ordering to physical pressure (Fig. 4).



The *B*20 crystal structure is interesting because it is chiral, allowing spin-orbit coupling to play a key role in electronic and magnetic properties. A large number of binary silicides and



germanides form in this crystal structure which is responsible for both helimagnetism and the formation of Skyrmion lattice phases that are ubiquitous in this family of materials⁸. In an initial series of polycrystalline samples, we have discovered that chemical substitution series between the non-magnetic small gap insulator RuGe (*B*20) and the diamagnetic metal CoGe, Ru_{1-x}Co_xGe, yields magnetic metals for a wide range of *x*. Large single crystals of this series were grown by the Bridgman technique and will allow us to map out the magnetic phase diagram.

Future Plans

Our future plans involve both the continued study of these materials, as well as to identify new materials for investigation, with a focus on the use of neutrons to probe the elastic and inelastic properties. The goal is to connect the results of neutron scattering

experiments to their novel emergent properties. The growth of high quality single crystals will continue to be an indispensable component to our research program.

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Stability, Structure, and Molecular Orientation in Organic Glasses Produced by Physical Vapor Deposition

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Program Scope

Organic glasses with high density, low enthalpy, and remarkably high kinetic stability can be prepared by physical vapor deposition (PVD).¹ We are investigating the extent to which high kinetic stability and tailored anisotropy can coexist in the same material. These experiments build upon the recent development of a high-throughput temperature-gradient methodology to efficiently prepare and characterize organic glasses. Using materials applicable to organic electronics, we are working to further our fundamental understanding of the vapor-deposited glasses and the amorphous state by pursuing the following objectives: 1) Utilize grazing-incidence and wide-angle x-ray scattering, and optical absorption and emission, to characterize vapor-deposited glasses. 2) Find and understand general trends in the properties of glasses prepared by depositing single and multiple component systems. We seek to identify the range of anisotropic amorphous structures that can be produced by PVD and develop the mechanistic understanding needed to predict the anisotropy produced by specific deposition conditions. 3) Build upon recent work showing that PVD can produce "stable glasses" with unprecedented thermal stability by investigating the extent to which stable glass packing can also increase photochemical stability and resistance to crystallization.

Recent Progress

Anisotropic Molecular Orientation. We have applied our high-throughput sample preparation protocol, developed with DOE support, to characterize glasses used in organic electronics.²

Figure 1 illustrates our protocol schematically. During vapor deposition, two copper fingers are heated or cooled to induce a temperature gradient across a bridging substrate. After deposition, different spots on the substrate are characterize measured to glasses prepared at many substrate temperatures on a single sample. Our approach provides a highly efficient method to investigate the impact of substrate temperature on glass properties, which we have previously shown to be a controlling in model factor glassformers.^{3,4}

Using our upgraded spectroscopic ellipsometer, we can detect dichroism



Figure 1. Top: A diagram of the temperature gradient sample holder. Bottom: Orientational order parameter for three linear molecules as a function of substrate temperature during vapor deposition, as determined by spectroscopic ellipsometry.

and quantify molecular orientation. By measuring the dichroism of a strong transition dipole along the long axis of the linear molecules, we are sensitive to the average orientation of the entire molecule. The orientation is quantified by calculating an orientational order parameter where vertically aligned molecules have an order parameter value of 1, horizontally aligned molecules have a value of -0.5, and randomly arranged molecules have a value of zero.

Figure 1 shows the trend in molecular orientation for three linear molecules used in organic electronics. At high substrate temperatures, ordinary glasses are prepared and molecules are isotropic. At slightly lower substrate temperatures, molecules show a slight tendency for vertical orientation, while at low substrate temperatures molecules show a strong tendency for horizontal orientation. This result demonstrates that a wide range of molecular orientations are accessible for a single molecule. Furthermore, all three linear molecules have the same trend in molecular orientation when the substrate temperature is scaled relative to their glass transition temperature, T_g. This suggests that orientation depends primarily on substrate temperature rather than the aspect ratio of the molecule. Simulations by collaborators Lyubimov and de Pablo suggest the orientation depends on the mobility of the surface and the structure of the surface of the equilibrium supercooled liquid.^{2,5} Additionally, we found that these organic electronic materials form highly stable glasses with similar trends in density and kinetic stability as previously observed in model glassformers.²

We have extended our studies of molecular component orientation to two systems by measuring the molecular orientation of DSA-Ph, a light emitter which can be highly anisotropic (Figure 1), in Alq₃, an isotropic host. This design mimics active layers in OLEDs, where a light emitter is dispersed in a host matrix to reduce concentration quenching. Remarkably, we observe the same trend in the molecular orientation of DSA-Ph in neat films and multicomponent films (Figures 1 and 2), with the features shifted to higher temperatures with increasing volume faction of Alq₃ (Figure 2). These data collapse when scaled



Figure 2. Orientational order parameter of DSA-Ph in films with different volume faction of Alq_3 .

by the T_g of the mixture, suggesting that the mobility of the material is the dominate factor in determining molecular orientation of an emitter in an isotropic host.

Anisotropic Molecular Packing. Previously, we have used X-ray scattering to investigate structural anisotropy in vapor deposited glasses.⁶ To extend this work, we have applied our high-throughput sample preparation technique (described above) to X-ray studies of anisotropic molecular packing in vapor-deposited glasses used in organic electronics. We have been awarded synchrotron beam time at the Stanford Synchrotron Radiation Lightsource (SSRL) to further our investigations.

We have characterized molecular packing in vapor deposited glasses of TPD using X-ray facilities on-campus and at SSRL.⁷ Figure 3 shows representative scattering patterns obtained from grazing incidence X-ray scattering (GIWAXS) measurements from SSRL for two TPD glasses prepared with different substrate temperatures. Variation in the scattering intensity indicates changes in the anisotropic molecular packing of the different glasses.

X-ray scattering measurements reveal that the molecular packing in TPD glasses varies from faceon to edge-on tendencies as a function of substrate temperature.⁷ These results, in conjunction with the orientation order parameter measured bv ellipsometry (Figure 1), give us a more complete picture of the structure of TPD glasses. As is illustrated schematically in Figure 3, at low substrate molecules preferentially temperatures are horizontally orientated with face-on packing. When $T_{substrate} = 315$ K, molecules are preferentially vertically orientated and are packed edge-on with respect of the substrate.

We have also made GIWAXS measurements on vapor-deposited glasses of DSA-Ph, another system of interest in organic electronics with tunable molecular orientation (Figure 1). Preliminary results suggest that DSA-Ph glasses show the same trends in molecular packing with substrate temperature as TPD, but are even more ordered.

Thermal stability. We have measured the thermal stability of vapor-deposited glasses of TPD, a hole transport material used in organic electronics, and discovered the transformation mechanism for these thin films.⁸ When heated above T_g , we found that vapor-deposited glasses of TPD transform to a liquid via constant velocity propagating fronts, as is illustrated in Figure 4.

Transformation fronts have previously been observed formers^{9,10} but for model stable glass are unprecedented in systems used for organic electronics. By combining a new, high-throughput annealing procedure with our previously developed high-throughput sample preparation, we systematically measured the effect of substrate temperature and annealing temperature on the thermal stability of the TPD glasses. This extended data range allowed us to deconvolute the effect of the mobility of the liquid and the structure of the glass, and we found that they are independent factors in controlling the thermal stability of TPD films. As shown in Figure 4, TPD films have similar front velocities and substrate temperature dependence model as glassformers, such as indomethacin (IMC), suggesting universal transformation behavior in stable, vapor-deposited glasses. These results may aid in designing active layers in organic electronics with increased thermal stability.



Figure 3. GIWAXS data and schematics illustrating the anisotropic molecular packing for TPD glasses prepared at two substrate temperatures. Schematics exaggerate the order in the films.



Figure 4. Top: Illustration of a stable glass transforming to a liquid via propagating fronts. Bottom: Free surface initiated front velocity of TPD and IMC glasses deposited at a range of substrate temperatures at several annealing temperatures, measured by ellipsometry.

Future Plans

For the next two years, we have the following priorities: 1) Characterize the molecular orientation and packing in vapor-deposited glasses of disc-shaped and nearly-spherical molecules to investigate the influence of molecular shape on anisotropy. 2) Using our granted SSRL beam time, characterize three molecules with GIWAXS and WAXS to further probe for structure-property relationships. 3) Study the molecular orientation of two component films with an anisotropic host material to investigate how the orientation of the host may influence that of the dopant. 4) Develop fluorescence measurements to characterize the molecular orientation of phosphorescent emitters at very low (~3%) concentrations in host materials.

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Program Title: Artificially Layered Superlattice of Pnictide by Design

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Program Scope

The goals of the program are to grow artificially engineered superlattices of pnictide materials by atomic layer-controlled growth, and to understand how structure property-relationships interact with the novel superconductivity in the pnictides so as to develop new understanding, applications, and devices. The critical scientific issues we will address include growth mechanisms, interaction between superconductivity and magnetism, interfacial superconductivity and physics of flux pinning in pnictide thin film heterostructures. We expect that this goal will also enable an understanding of the fundamental heteroepitaxial growth of intermetallic systems on oxide surfaces and role of interfacial layers in a sufficiently general way that can be applied broadly to many different material systems.

The discovery of superconductivity with transition temperatures of 20K-50K in iron-based materials has initiated a flurry of activity to understand and apply these novel materials. The superconducting mechanism, the structural transitions, the magnetic behavior above and below T_c , the doping dependence, and the critical current and flux-pinning behavior have all been recognized as critical to progress toward understanding the pnictides. A fundamental key to both basic understanding and applications is the growth and control of high-quality epitaxial thin films and superlattices with atomic layer control. The ability to control the orientation, the strain state, defect and pinning site incorporation, the surface and interfaces, and the layering at the atomic scale, are crucial in the study and manipulation of superconducting properties.

An important characteristic of the Co-doped BaFe₂As₂ (Ba-122) material is the relatively low values of doping required to produce superconductivity. This leads to homogeneous films, and similar lattice constants between differently doped films, and great potential for epitaxial superlattices. The 122 materials share the fundamental iron-containing planes that are believed to be responsible for superconductivity, and they potentially all share the same basic mechanism of superconductivity, with a leading candidate being s^{+-} pairing between electron and hole pockets at the zone center and boundary. All share the five Fe 3*d*-orbitals important in the electronic structure, leading to a richness that has great potential for manipulation. In addition, the likely coexistence of magnetism and superconductivity for low-doping, and the nearby structural transitions in the intermediate-doping region, offer great flexibility in the design of new superlattices of, for instance, doped 122 and perovskite oxides, 122 layers of different doping levels, and doped 122 layers with the semi-metallic undoped parent compound.

We are guided to the main goals by our understanding developed over the last three years in relating pnictide structural and superconducting properties. The new film growth methods used in this project enables us to not only resolve these uncertainties, but also to design and synthesize new pnictide atomic layered structures that explore the limits of this material's superconducting properties. The **thrusts** of our project are:

- (1) Atomic-layer-controlled growth of artificially engineered superlattice synthesis
- (2) Designing interfacial superconductivity at pnictide and FeSe interfaces.
- (3) Investigation of interaction between superconductivity and magnetism by proximity effect
- (4) Understanding and control of flux-pinning mechanisms
- (5) Study of growth mechanisms of heteroepitaxial superlattices and artificial pinning centers

Recent Progress

1. Atomic-layer-controlled growth of Ba(Fe_{1-x}Co_x)₂As₂ films

BACKGROUND

The discovery of superconductivity with transition temperatures of 20K-50K in iron-based materials has initiated a flurry of activity to understand and apply these novel materials. The superconducting mechanism, the structural transitions, the magnetic behavior above and below T_c , the doping dependence, and the critical current and flux-pinning behavior have all been recognized as critical to progress toward understanding the pnictides. A fundamental key to both basic understanding and applications is the growth and control of high-quality epitaxial thin films and superlattices with atomic layer control. The ability to control the orientation, the strain state, defect and pinning site incorporation, the surface and interfaces, and the layering at the atomic scale, are crucial in the study and manipulation of superconducting properties.

DISCUSSION and FINDINGS

We have studied the influence of perovskite substrate surface termination on the properties of superconducting pnictide thin films to understand the thermodynamic equilibrium between at pnictide thin film/oxide interfaces. To explain the dependence on substrate surface termination, we proposed the schematic growth model of Co-doped $BaFe_2As_2$ described in Fig. 1. Due to the different crystal structures, the interface with SrO terminated substrate will have high interfacial energy with the film, and need additional stabilization through surface reconstruction. However, Ba layer as the 1st layer on top of TiO₂ surface maintains the perovskite stacking of SrTiO₃. We find in this case that the unit cell of

BaFe₂As₂ grows epitaxially after reaching interfacial equilibrium. In contrast, it is relatively hard to reach phase stability at the interface between Ba122 and SrO surface because arsenic is volatile as a starting layer. Fe and Co elements may interdiffuse/intermix with Ti at the surface of SrTiO₃ to move toward thermodynamic stability. We have grown Co-doped pnictide thin films on $SrTiO_3$ (001) substrates with the controlled termination states. As-received SrTiO₃ substrates have the mixed termination states of both TiO₂ and SrO, whereas the single TiO₂ termination can be attained by chemical etching treatments using buffered hydrofluoric (BHF) acid etchant.



Figure 1. Schematic model of $BaFe_2As_2$ thin film on (a) TiO_2 and (b) SrO-terminated $SrTiO_3$.

Scanning transmission electron microscopy

(STEM) measurements show that the interfacial layer depends on the surface termination of $SrTiO_3$ substrates. In TiO₂-terminated regions, a Ba layer was imaged as the first interfacial layer, whereas a FeAs layer was shown on SrO-terminated regions as shown in Fig. 2. Note that one unit-cell of BaFe₂As₂ is consisted of the stacking structures of Ba-AsFeAs-Ba-AsFeAs-Ba. Therefore, clear and abrupt interface for epitaxial BaFe₂As₂ film growth can be apparently found on TiO₂-terminated SrTiO₃ with less diffusion. On the other hand, there is more diffusion with broader interface on SrO surface terminated SrTiO₃ is significant higher than mixed surface terminated SrTiO₃. In particular, the difference in T_c is

much more pronounced in ultrathin films because atomically sharp interface can be formed and chemical diffusion is also suppressed with less reaction layer.

Importance of findings both from experimental and theoretical perspectives:

Based on theoretical calculations and STEM imaging at the $Ba122/SrTiO_3$ interfaces with the surfaces termination control, we have confirmed that non-perovskite Ba-122 films shows atomically sharp and well-defined interfaces with TiO₂-terminated STO perovskites. This interface engineering is not only



FIG. 2. High resolution STEM ABF and HAADF images for 24 nm thick Ba-122 films on (a) TiO_2 -terminated STO by BHF etching and (b) mixed surface termination of as-received STO. There is a clear interface with Ba layer as a 1st layer on top of TiO_2 terminated STO, whereas SrO surface termination has blurred interface with more diffusion.

limited to STO substrates, but can also be used to explore the STO buffer layer on various perovskite substrates with different lattice parameters and artificially layered superlattices. We believe that deliberately strained STO template layer with TiO₂ surface termination can also open many possibilities for fundamental research for strain engineering in monolayer FeSe. It be tailored can to

improve performance and new functionalities of Fe-based superconducting thin films with engineered interface of various perovskite oxide substrates.

Future Plans

(1) <u>Superconductivity and magnetism at atomically abrupt Pnictide interfaces</u>

The interaction between magnetism and superconductivity is central to the physics of pnictide superconductors, as well as other modern superconductors with potential applications. We have demonstrated that epitaxial heterostructures with sharp interfaces can be made between the optimallydoped material Ba(Fe,Co)₂As₂ and other doping levels, as well as insulators such as SrTiO₃, and metallic ferromagnets such as Ni, Co, and Fe. We will compare two different Normal Metal (N) / Superconductor (S) configurations, using the same superconducting layer and changing the N layer properties to determine the interfacial interaction of superconductivity and magnetism. The SC material will be fixed at optimal doping Ba(Fe_{0.92}Co_{0.08})₂As₂ (x=0.08), with maximum T_c (see Fig. 3, the phase diagram for Ba-122 with Co doping). In the first N_u (undoped normal metal) /S (superconductor) interface, the normal metal (N_u) will be undoped BaFe₂As₂ in which the AFM-SDW correlations dominate. In the second N_o (overdoped normal metal) /S (superconductor) interface, the normal metal (N_0) will be heavily doped Ba122 (x=0.20), a paramagnetic metal with no AFM ordering and no SC transition. In Fig. 3 the blue, purple and red arrows represent, respectively, the low doping, optimally doping and over-doping Ba-122 compounds, whose relative interaction we propose to study. Any weakening or enhancement of superconductivity in these systems (i.e., seen as a decrease or increase of T_c) will provide a straightforward demonstration of the competitive nature or coexistence of the two long-range orders. The comparison between the two heterostructures will also determine if magnetism has an important role as mediator in the interaction that drives superconductivity in pnictides.

(2) Designing interfacial superconductivity at FeSe interfaces

We plan to grow FeSe monolayers on different ferroelectric surfaces in collaboration with Lian Li's group at UW-Milwaukee, exploiting our group's long history in the preparation of strained ferroelectric films. The motivation here is the suggestion that screening by ferroelectric (FE) phonons may be responsible for the greatly enhanced T_c in monolayer FeSe grown on SrTiO₃ (STO). Such FE phonons in STO are relevant at temperatures below ~100K when the dielectric constant becomes quite large, but are present already at higher temperatures in other FE materials such as BaTiO₃.

Alternative ferroelectric surfaces will be explored starting with biaxially strained epitaxial thin films of Ti- surface terminated BaTiO₃ on rare-earth scandate (*REScO*₃) substrates with different lattice parameters. These new substrates include seven different *REScO*₃ compositions with lattice constants that vary in 0.01 Å increments. High quality single crystal BaTiO₃ thin films are necessary, as bulk single-crystal substrates of BTO crack easily under thermal cycling due to the phase transitions. The strain state and remnant polarization of the strained BaTiO₃ thin film prior to FeSe monolayer deposition can be controlled by using substrates with different lattice mismatch, keeping the FE film thickness less than the critical one for relaxation. Such film strain will change the frequency of the zero-point FE phonon mode, the mode suggested as responsible for the dielectric screening, offering a new parameter to control the dielectric screening of the FeSe film. In addition, the final surface termination of these FE films (i.e., AO or BO₂, or mixed) can be controlled by *in situ* RHEED before the FeSe monolayer films are grown, offering an additional degree of freedom as compared to single-crystal substrates. We also plan to study the electronic band structures of monolayer FeSe on strained SrTiO₃ template using our ARPES system.

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Using Multi-Phase Energetic Precursor Jets to Enable New Modes of Focused Electron Beam Induced Processing (FEBIP)

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Program Scope

Current program focuses on developing new capabilities and establishing the fundamental understanding of using energized gas and liquid phase jet precursor delivery for FEBIP, including:

<u>Gas Jet Molecular Modeling and Simulations</u>: We are developing a novel approach based on dynamic adaptation of number of simulated particles in a computational cell, or Adaptive Direct Simulation Monte Carlo (Adaptive-DSMC), which has a range of applicability and validity across the entire range of flow regimes realized in Gas-Jet-Assisted FEBIP. First set of comprehensive gas-jet simulations under relevant experimental conditions have been performed, which demonstrated – for the first time - the impact of supersonic jet focusing on localization of molecular flux on the substrate, and confirmed via complimentary experiments on PMMA (contaminant) ablative removal ("cleaning") and high purity tungsten nanostructure growth from an organometallic $W(CO)_6$ precursor with minimal entrapment of C/CO ligands.

<u>Energized Gas Jet Assisted Electron Beam Etching (FEBIE) of Graphene</u>: We demonstrated that use of a microjet enabling supersonic delivery of heated oxygen yields a substantial improvement in the Focused Electron Beam Induced Etch (FEBIE) rate and parasitic carbon contamination removal, which provide a path to overcome intrinsic challenges of using FEBIE as a "direct write" tool for nanoscale patterning of graphene electronic devices.

Dynamic Modulation Graphene Electronic Properties Using FEBID Carbon Doping: We discovered a new phenomenon of controllable carbon doping of graphene, which allows tuning of local electronic properties of a graphene conduction channel using focused electron beam induced deposition (FEBID). An "n-p-n" junction on graphene conduction channel is formed near the source and drain metal contacts by partial carbon deposition of the FEBID carbon atoms, which are physisorbed and weakly bound to graphene and diffuse towards the middle of graphene conduction channel due to their surface chemical potential gradient, resulting in negative shift of Dirac voltage. In combination with using energetic inert gas jets for locally tuning the FEBID carbon dopant distribution and transport properties, these findings establish a new route to resist-free, "direct-write" functional patterning of graphene-based electronic devices with potential for on-demand re-configurability.

<u>Electrospray-assisted Focused Electron Beam Induced Deposition (ES-FEBID) from Liquid</u> <u>Phase Precursors</u>: We invented and experimentally demonstrated a fundamentally new approach to FEBID using liquid phase precursors delivered using the jet/droplet electrospray process into a vacuum environment of deposition chamber. Not only this process dramatically expands the range of precursors available for FEBID, but also allows for dynamically controlled formation of a large in extent, stable thin liquid film enriched with the precursor on the surface of deposition substrate, which allows for scalable formation of nanostructures over large surface areas.

Recent Progress

Adaptive DSMC for Gas-Jet Simulation: New Technique Development and Validation. Gas jet interactions with the substrate surface are foundational to FEBIP. Therefore, complimentary gas-

jet simulations and experiments have been performed to spatially and quantitatively characterize the substrate properties due to impingement from a supersonic gasjet. The Adaptive-DSMC unique capability is to transcend several orders of magnitude variation in the molecular mean free path upon gas jet introduction from the external supply reservoir to the vacuum environment of the deposition chamber, ultimately predicting the spatially resolved molecular flux and impingement energy on the surface. The strategy behind the adaptive algorithm is to use the "cell factor" the ratio between simulation particles



Fig. 1 (Clockwise): Adaptive DSMC simulation of Ar gas-jet emanating from a 75 μ m ID nozzle onto an evacuated substrate tilted at 45°. The magnitude of the cell factor defines the isolines bounding different flow regimes (continuous, transitional, rarefied) withib computational domain. The ultimate result is prediction of the magnitude and distribution of the molecular flux on substrate.

and physical particles – to vary from one computational cell to the next. This allows each cell to hold a computationally practical number of particles for each regime and the same molecular physics to be applied to each regime. The Adaptive-DSMC has been applied to simulate experimental conditions typically used in our Gas-Jet FEBID with results shown in Figure 1, which are in excellent agreement with experiments.

<u>Supersonic Gas Jet Assisted Electron Beam Etching of Graphene</u>. Along with a focused electron beam induced deposition (FEBID) technique, focused electron beam induced etching (FEBIE) also provides a superior lithographic capability to controllably manipulate material structure and properties. Especially, it is very promising when applied to 2D monolayer materials, such as

graphene, whose electronic properties can be changed from semi-metallic to semiconducting by nanoscale modification of its geometry to nanoribbons. We investigated the utility of energized (heated) oxygen micro-jets for accomplishing high resolution FEBIE with minimal parasitic carbon deposition and fast etching time. Using



Fig. 2: Line etching of graphene with different flow rates of oxygen micro-jets, 3 sccm, 5 sccm, 7 sccm and 10 sccm (from the left to the right), at two different jet temperatures: a) room temperature ($24 \, ^{\circ}$ C) and b) heated to 100 $^{\circ}$ C. Scale bar: 4 um.

10 µm ID injection nozzle we first optimized the electron irradiation zone in order to determine the best location surrounding the center of an oxygen jet impact area for FEBIE. At a fixed nozzle position and oxygen jet conditions (10 sccm & T_{jet} ~24°C), graphene etching was successful at all locations within ± 20 µm from the center point of the jet impact area with the point of direct jet line-of-sight to be most optimal for etching. Using electron beam current~ 250 pA, energy~ 10 kV, and dose~ 2e19 e⁷/cm², line etching was performed with oxygen flow rates from 3 sccm to 10 sccm at two distinct gas-jet temperatures, 24 °C vs. 100 °C. Fig. 2 shows AFM images after FEBIE. At both gas jet temperatures, increasing flow rates from 3 sccm to 5 sccm improved the etching outcome and reduced the thickness of 'halo' deposits. Further increase of oxygen flow rates degrades etching quality due to increased chamber pressure, promoting e-beam scattering. Compared to the etching result with room-temperature oxygen jets, heating jets to 100 °C led to improved etching (Fig. 2b). Specifically, with 5 sccm oxygen micro-jets, etching depth was measured ~ 4 nm for the heated vs ~ 3 nm for the unheated jets. This indicates that thermally energized, oxygen micro-jets can overcome many challenges (poor resolution, long etching time and parasitic carbon deposition) of FEBIE.

Dynamic Modulation of Graphene Electronic Properties Using FEBID Carbon Doping. Controllable carbon doping using FEBID was demonstrated to modulate electronic properties of graphene (Fig. 3), both the local formation and evolution of the p-n junction and long-term stabilized modification of its doping state. Initially, CVD graphene in electronic devices is pdoped by PMMA residues from the graphene transfer process and lithography steps. Upon

electron beam treatment with a low electron dose ~1e18 e /cm², locally concentrated FEBID carbon is deposited near the graphene-metal junction, where the primary electron beam strikes, which establishes an "n-p-n" junction on the graphene channel. At room temperature, the weakly interacting FEBID carbon atoms diffuse towards the middle of the graphene channel due to their surface concentration gradient and rearrange their structure reducing the level of initial graphene p-type doping. When a high electron dose \sim 1e19 e⁻/cm² treatment is used. FEBID carbon film is deposited on the graphene channel uniformly throughout with sufficiently high surface density, which completely reverses doping state of the graphene channel from p-type to n-type. When combined with oxygen-jet FEBIE, these experiments not only highlight a unique capability for tuning the graphene's electronic properties via controlled carbon FEBID doping, but also suggests a new possibility of using energized gas jets for local control of doping state by selective carbon removal.





Fig. 3. (a) Schematic of FEBID treatment of graphene device channel via irradiation of metal contacts. (b) Change of the electric transfer characteristic (R_{tot} vs. V_{bg}) upon FEBID of carbon, showing dynamic control of doping state of the graphene channel.

Electrospray (ES)-Jet-Assisted FEBID from Liquid Phase Precursors. Exploratory work has been

conducted to investigate the use of liquid-phase ionic precursors delivered via nanoelectrospray (nanoES)-driven jets coupled with FEBID to form deposits upon e-beam mediated electrochemical reduction of precursor. The process of nanoES-FEBID is described in Figure 4. A pre-filled pulled glass capillary is mounted in the SEM chamber and the tip is brought near to the substrate. A high-voltage power supply is used to apply a positive bias to the capillary, relative to grounded substrate, to deliver liquid precursor via the electrohydrodynamic Taylor cone-jet. Thin liquid pool is achieved by initiating spray and adjusting the potential and the



Fig. 4: (a) Schematic of ES-Jet-FEBID. A pulled glass capillary emitting nanoelectrospray sustains a pool of liquid that supplies precursor to the deposition site. Deposits grow from the deposition site, forming pillars if the beam is held in-place. (b) A silver pillar, 17 μ m base width and 39 μ m height, deposited from silver nitrate precursor. (c) SEM image of nanoES Taylor cone-jet from a 2.5 μ m outer diameter tip. (d) Thin liquid film is achieved by forming a droplet of desired width, then reducing the spray voltage until a sufficient thinning occurs via solvent evaporation.

tip/substrate gap until a liquid pool of desired width is observed. Upon exposure to the electron beam at 25 keV and 13.4 nA, silver and carbon nanopilar deposits have been rapidly grown at the rate exceeding by 4 orders of magnitude the current state-of-the-art for gas-phase FEBID.

Future Plans

Energetic Gas Jet FEBID & Simulations. Two key parameters of the energetic gas jet - the molecular flux on the substrate and internal energy of precursor molecules due to gas heating at the nozzle – will be experimentally correlated with and tuned to affect the key deposition parameters, such as substrate temperature and the precursor sticking coefficient. In concert with these experiments, adaptive-DSMC modeling will be performed to be able to relate the experimentally measured macroscopic properties to fundamental molecular properties of the precursor species, substrate material and jet flow regime. Ultimately, this basic understanding will provide a foundation for in silico optimal design of energetic gas-jet assisted FEBIP process. Energized Gas Jet FEBIE of 2D Materials. Fundamental limits will be assessed to provide a complete map of FEBIE outcomes (etch rate, spatial resolution, and extent of parasitic carbon deposition around etched domains) as function of experimental conditions for etchant delivery by the gas jet for graphene and other emerging 2D electronic materials (MoS_2 , hBN, etc). Adaptive DSMS simulations will be used to aid in interpretation of experimental observations, which will ultimately enhance our first-principles understanding of micro-jet assisted FEBIE.

<u>ES-Jet-Assisted FEBID from Liquid Phase Precursors.</u> The focus is on gaining fundamental understanding of physico-chemical mechanisms underlying liquid phase FEBID through probing interactions between primary, secondary and solvated electrons with electrified precursor liquids.

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Forces, Crystallization, and Assembly in Nanoparticle Suspensions

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Program Scope

In the past decade, an astounding variety of intricate nanostructures, having at least one dimension of 100 nm or less, have been synthesized via solution-phase techniques. These nanostructures will benefit numerous applications in energy technology. It has been emphasized that the sizes, shapes, phases, and assembly or dispersion of the nanoparticles can significantly impact their performance. A deep, fundamental understanding of the phenomena that promote shape-selective growth and assembly in these syntheses would enable tight control of nanostructure morphologies in next-generation techniques and allow for the synthesis of more elaborate nanostructures. In many systems, structure-directing agents (SDAs) are used. These agents can range from small monomer molecules to high-molecular-weight polymers. Although there is a great deal of experimental evidence indicating that SDAs can play a pivotal role in selectively producing various nanostructures, their exact role remains elusive.

In this work, complementary theoretical and experimental methods are used to quantify the binding of SDAs to coinage-metal surfaces and to resolve mechanisms of shape-selective growth. On the theoretical side, first-principles, dispersion-corrected, density-functional theory (DFT) and classical molecular dynamics (MD) simulations are employed to quantify binding energies, as well as mechanisms by which solution-phase growth occurs. Two experimental platforms – isothermal titration calorimetry and *in-situ*, liquid-phase, high resolution transmission electron microscopy – are being developed and used to quantify SDA binding energies to various nanostructures and provide a real-time, *in-situ* view of nanostructure growth.

Recent Progress

Our recent theoretical work is inspired by an experimental study of Xia et al. [1], who probed the growth of cubic Ag nanocrystal seeds in ethylene glycol (EG) solvent polyvinylpyrrolidone using (PVP). PVP is a well-known SDA for promoting {100}-faceted Ag nanocrystals and this capability has been attributed to preferential binding of PVP to Ag(100) [2]. They found that {100}-faceted seed cubes continue to grow as cubes, if the concentration of PVP is sufficiently high. Below a critical PVP concentration, the cubic seeds evolve into cuboctahedra and



{111}-faceted octahedra. These relatively large nanostructures (40-100 nm size range) are likely controlled by kinetics and the kinetic Wulff construction can be used to predict shape evolution.

We used MD simulations and theory to probe the octahedron-to-cube transition seen experimentally by Xia *et al.* [1]. Our MD simulations are based on an empirical potential that we fit to our results from dispersion-corrected DFT [3-5]. Using MD, we calculated potentials of mean force to obtain the free-energy profiles for Ag atoms to approach PVP-covered surfaces in EG solution. We also quantified the mean-first passage time for solution-phase Ag atoms to reach Ag(100) and Ag(111) facets. We find that PVP induces kinetic Ag nanocrystal shapes by regulating the relative Ag fluxes to these facets. Strong PVP binding to Ag(100) leads to a larger Ag flux to Ag(111) and cubic nanostructures through two mechanisms: enhanced Ag trapping by more extended PVP films on Ag(111) and a reduced free-energy barrier for Ag to cross lower-density films on Ag(111). Figure 1 shows our predicted shapes for Ag nanocrystals with different PVP coverages and chain lengths. These are consistent with experiment.

Our recent experimental progress has concentrated on three primary aspects: (i) synthesis of phase-pure, high yielding Ag cube and octahedron syntheses: (ii) development of a robust ITC method for evaluating the thermodynamic parameters for PVP binding through displacement titration of thiols; (iii) influence of small PVP-like molecules on the growth of Ag cubes. Additional topics being investigated but not discussed here include the synthesis of PVP "dimers" with varying alkyl spacers and the quantification of PVP on Ag nanoparticle (cubes and octahedron) by gel permeation chromatography, which will be used to quantify how many ligands are displaced.

High yielding synthesis of cubes [6] and octahedra [7] were achieved with minor modification of published protocols (Figure 2A and B). These particles were filtered to produce monodisperse particle Ag populations, followed by numerous washing to remove excess and weakly bound PVP from the surface. We have previously demonstrated that thiol adsorption on coinage metal nanoparticle surfaces provides strong sigmoidal signals the ITC due the strength of the Au-S bond [8]. Since a colloidal nanoparticle surface is never free of adsorbate, we developed a displacement titration method using



Figure 2. (A-B) SEM micrograph of Ag cubes and octahedral, respectively. (C) titration of 2.86 mM 3-mercaptopropionic acid to PVP-covered. Ag cube (0.22 mM of surface Ag atom) (D) proposed relationship between K_{app} and concentration of low affinity ligand.

thich to quantify the thermodynamics of PVP binding by the following equation, $K_{app} = \frac{K_{high}}{1 + K_{low} [L_{low}]}$ where K_{app} is the measured apparent affinity, K_{high} is the affinity of thich for

Ag, K_{low} and L_{low} represent the affinity of PVP for Ag and the concentration of low-affinity ligand in the calorimeter cell [9]. **Figure 2C** demonstrates the adsorption of thiol to a minimally PVP-covered surface without PVP addition to the calorimeter. On basis of two additional experiments, the form of K_{app} with $[L_{low}]$ will follow the trend shown in **Figure 2D**. K_{high} and K_{low} are expected to be extracted by fitting the equation to various K_{app} evaluated by the single

independent binding depending on $[L_{low}]$. We believe these displacement titration calorimetric measurements using thiols as a probe is the best experimental approach to measuring reliable thermodynamic binding parameters of PVP to Ag, and these K_{low} values can be compared with values determined by Fichthorn.

While it has been demonstrated that low molecular weight PVP (< 10 K) is unable to promote the formation of Agcubes, we investigated the influence of small molecule PVP-like analogs on the synthesis of Ag cubes. These small molecule analogs are similar to those studied using DFT by the Fichthorn group [5]. Figure 3 demonstrates that the smallest PVP analog (2-pyrrolidone (2P)) has the greatest influence on the yield of cubic particles. This is a particular interesting result because it demonstrates that the number of contacts per PVP chain is critical for shape control and upon the addition of a molecule like 2P that is small enough to access the growing Ag surface and is able to displace some PVP chain surface interactions which reduces shape control. This effect is 2P concentration dependent (data not shown). The lack of influence of the presence of 1-(ethyl/octyl/dodecyl)-2-pyrrolidone is associated with the steric effect associated with the



Figure 3. SEM micrographs of Ag particles synthesized by the polyol method with 147 mM PVP (55K) and 1147 mM of (A) 2-pyrrolidone; (B) 1-ethyl-2-pyrrolidone; (C) 1-octyl-2-pyrrolidone; and (D) 1-dodecyl-2-pyrrolidone.

alkyl backbone which doesn't enable access to the surface and therefore has limited influence on particle growth.

Future Plans

A number of activities are planned for the upcoming year that are already underway. A major effort is centered around using our recently developed force field to describe aspects of PVP-mediated nanocrystal growth: calculating solid-liquid interfacial free energies to predict thermodynamic Wulff shapes of Ag nanocrystals, examining the kinetics of restructuring of small Ag nanocrystals to understand how nanocrystal shape depends on nanocrystal size, investigating the nucleation mechanisms of Ag nanocrystals, and following up on Rioux's experimental results. Rioux will continue to develop the displacement titration method for octahedron particles detailed in Figure 2, as well as quantify the coverage of PVP on Ag cubes and octahedron. Another ongoing effort focuses on characterizing the binding of self-assembled hexadecylamine layers to Cu(100) and Cu(111) to understand the workings of this small-molecule SDA.

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Understanding the Role of Viscosity and Deposition Rate during Vapor-Phase Free Radical Polymerization onto Liquid Surfaces

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Program Scope

Our goal is to uncover the mechanisms associated with polymer nucleation, particle growth, and film formation at the vapor/liquid interface during initiated chemical vapor deposition (iCVD) onto liquid surfaces. The iCVD process is a solventless free radical polymerization technique that is traditionally used to deposit thin polymer coatings onto solid substrates from acrylate and acrylamide precursors.^{1,2,3} In the iCVD process, monomer and initiator molecules are flowed into a vacuum chamber where the initiator molecules are broken into free radicals by a heated filament array. The initiating radicals and monomer molecules diffuse to the surface of the cooled substrate and polymerization occurs via a free radical mechanism. We have recently shown that liquids with negligible vapor pressures such as ionic liquids (ILs) and silicone oils can be used as substrates in the iCVD process (Figure 1).^{4,5,6,7} The liquid surface provides new initial conditions for growth due to the mobility of the polymers on liquid surfaces. Our goal is to

uncover the molecular mechanisms that govern polymer nucleation and growth at the vapor/liquid interface bv systematically studying how different parameters such as liquid viscosity and polymer deposition rate affect the structure and size of the films and particles.



Figure 1. (A) Deposition of fluoropolymer results in a polymer film on silicone oil, (B) whereas deposition of poly(4-vinylpyridine) results in distinct polymer particles. (C) SEM image confirms deposition of distinct particles.

Recent Progress

During this research period, we focused on the polymerization of cross-linked polymers. We had previously found that linear polymers form films or particles on liquid surfaces.⁸ The morphology depends on the surface tension interactions between the polymers and the liquid surfaces, which can be quantified by a spreading coefficient. Systems with positive spreading coefficients form films and systems with negative spreading coefficients form particles. For the past year, we studied the deposition of cross-linked polymers at liquid surfaces since cross-linked polymers have less mobility than linear chains and therefore the dynamics will be different. Our results were interesting. We found that although the spreading coefficients of these cross-linked systems predict the formation of particles, we instead observe the formation of microstructured films. These microstructured films are unique only to cross-linked systems.

We systematically studied the deposition of the cross-linked polymer, poly(ethylene glycol diacrylate) (PEGDA), onto a range of silicone oils with varying viscosities. We used scanning electron microscopy to examine the microstructured films and we found that the films contained micron-sized coral-like microstructures that were comprised of spherical aggregates. We examined the chemical composition of the films by Fourier transform infrared spectroscopy and we found that the microstructured films are composed of homopolymer PEGDA.

We examined the growth on 5, 100, 500, and 5000 cSt silicone oil. Our data showed that the microstructured films grow by simultaneous polymer aggregation at the liquid surface and wetting of the liquid on the growing aggregates. Atomic force measurements and SEM images showed that the microstructures decreased in size with increasing liquid viscosity. This decrease in the feature size is due to slower rates of polymer diffusion resulting in less aggregation on the liquid surface. This also leads to less void space between the microstructures and therefore a decrease in the thickness of the microstructured films with increasing liquid viscosity. The films formed on the high viscosity (5000 cSt) silicone oil were smooth due to very slow diffusion of the polymer at the liquid surface. (Figure 2)

Increasing the liquid viscosity decreases the diffusion rate of the polymer on the liquid surface, but also decreases the wetting rate of the liquid on the polymer. We therefore studied the effect of the polymer deposition rate in order to determine which effect dominates the growth mechanism of the films. Increasing the polymer deposition rate increases the molecular weights of the nucleated chains which diffuse slower on the liquid surface. We examined the growth on 5, 100, 500, and 5000 cSt silicone oil. At every viscosity, increasing the deposition rate decreased the roughness of the film and decreased the total film thickness. Since the wetting rate of the liquid on the polymer is constant at the same liquid viscosity, the changes in the film morphology on the same viscosity liquid with increasing deposition rate demonstrates that the growth of the microstructured films is dominated by the diffusion and aggregation of polymer at the liquid surface.



Figure 2. SEM images of the bottomsides and crosssections of PEGDA films removed from the silicone oil as a function of viscosity.

In addition to PEGDA films, we also created cross-linked copolymer films by depositing 2-hydroxyethyl methacrylate (HEMA) cross-linked with EGDA (P(HEMA-co-EGDA)) and 1-vinyl-2-pyrrolidone (VP) cross-linked with EGDA (P(VP-co-EGDA)). The copolymer films also contain microstructures.

Future Plans

Our future goal is to study the deposition of non-cross-linked polymers onto liquids. The deposition of non-cross-linked polymers leads to the formation of nanoparticles. We plan to study the parameters that affect the nucleation and growth of these particles. We will systematically study the particle size and polydispersity as a function of the viscosity of the liquid and the deposition rate. Our data will be compared to the data for cross-linked systems in order to understand how polymer diffusion is affected in our system.

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Nanoscale Selective Growth and Microstructural Control of III-nitride Growth

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Program Scope

Selective area growth (SAG), a technique using lithography to mask and expose portions of surface to direct vaporphase precursors to crystallize on specific surface sites, has become a powerful and versatile method to reduce the dislocation density in heteroepitaxy. ¹⁻³ A reduction of dislocation density by a factor of 10 to 100 in SAG has been accomplished by dislocation blocking and bending. ^{4, 5} With the advance in lithography, the concept of SAG has also been



Figure 1 (a) A schematic drawing illustrating the concept of dislocation existing growth region from geometry-based trapping. ⁸ (b) a cross-sectional TEM showing nanoscale SAG of dislocation-free InGaN. ⁹

applied to nanoscale. In the nanoscale SAG, aspect ratio trapping (ART), ⁶⁻⁸ the use of growth channels or constructs that have a high aspect ratio and small cross-section (compared to the motion of dislocations) to trap the dislocations, has been developed. An example of using ART to prepare dislocation-free, fully relaxed InGaN nanorods is shown in Figure 1(b) based on our previous DOE EBS project.⁹

However, other than the dislocation reduction mechanism mentioned above, several fundamental questions related to synthesis science in the nanoscale SAG need to be addressed. (1) How does nanoscale constriction in one direction impact the microstructure evolution in the other orthogonal directions? In the vertical epitaxial direction, the nanotrenches would act like a "roller press" that plays an active role in "forcing out" defects in heavily-mismatched growth in the vertical growth direction. Yet there is little knowledge regarding the coalescence dynamics along the lateral direction over micrometer scale. (2) How does the presence



Figure 2. A schematic drawing of selective growth in a nano-trench

of nanoscale geometric boundaries affect the crystallographic orientation in selective area epitaxy? Is it possible to influence if not direct the crystallographic orientation by the geometric shape of the nano-trenches?

Within the scope of this project, we propose to investigate the fundamental dynamics of vertical and longitudinal growth evolution in the nano-trenches. Further, the possibility to guide and direct crystal orientation with amorphous dielectric nano-trenches, in a way similar to graphoepitaxy, ¹⁰ will be explored. We believe that SAG in a nano-trench would be a perfect test ground to understand the role of layer-dielectric interaction. InN, of which recent study has shown superior transport properties in defect free nanowires, ¹¹

is chosen as a case study to demonstrate the efficacy and unveil the science in nanoscale SAG.

Recent Progress

A. Evolution selection growth

We have recently demonstrated single crystal GaN growth on amorphous $SiO_2/Si(100)$ template.¹² For a material to transform from amorphous to single crystalline, it requires effective reduction of degree of freedom (DOF) in atomic/grain alignment from 3 (the three Euler angles) to 0. We succeeded in doing so by combining conventional micronsize SAG with a phenomenon called "evolutionary selection" (ES)¹³ in material deposition. In our lab, we prepared special growth tunnels described in Figure 3. We sputtered AlN on SiO₂/Si(100) substrates which exhibits a textured microstructure (preferred AlN (0001) orientation; this process helped to reduce the DOF from 3 to 1, leaving the in-plane rotation as the remaining DOF. Using polycrystalline AlN as both a structural mold and growth seed, we



Figure 3 (a) Illustration of the concept of ES growth from a textured thin film (red layer) to produce single-crystal layer (blue region), (b) the processing sequence to carry out SAG ES growth. ¹²

fabricated micron-size SiO₂ tunnel structures that allow for selective area lateral growth with confinement in both horizontal and vertical directions. During the SAG process, GaN grains grow out of the sidewall of the textured AlN films and undergo a 2nd evolutionary selection. After the selection, the DOF is reduced to 0 and GaN becomes single crystalline within a few micrometers. In this demonstration, the horizontal ES growth by SAG was used for facilitate the reduction of DOF from 1 to 0. A synchrotron micro-focused XRD was exploited to study the evolutionary selection grown GaN on SiO₂.¹⁴ Theoretical modeling of the 3-dimensional confined SAG within a tunnel was carried out. ¹⁵ The gas flow regimes and mass transport through laterally and vertically confined masks were analyzed. The full understanding and control of the ES growth technique is expected to enable a scalable and effective method for integration of device quality semiconductor crystals with non-crystalline substrates, and further apply the use of channel confined masks to achieve other desirable growth configurations. The knowledge of evolutionary growth can enlighten us to pursue further in the nano-scale SAG regime. We believe that using nano-trenches, it will be possible to carry out orientation selection with grain alignment directed by nano-walls to reduce the degree of freedom in crystal orientation.

B. Nanoscale selective area growth (SAG) of InGaN nanorods

GaN-based light emitting diodes (LEDs) have attracted intense focus for many years due to the prospect of solid-state lighting. The internal quantum efficiency of planar

GaN-based LEDs drops precipitously towards longer wavelengths as the In composition increases, a phenomenon known as the "green gap". In our lab, we addressed the intellectual impasse of creating device quality, high indium content InGaN by a combination of interference lithography (IL) to create nanoscale features with a special pulsed flow modulation technique to enhance the surface diffusion during selective area growth of InGaN.⁹ We prepared InGaN nanorods as a nano-template for growing higher In composition InGaN nano-LEDs. We studied the mechanism for improving the selectivity of InGaN nanorods during selective area growth. The selectivity was improved by enhancing the diffusion length of Ga precursor on SiO₂ with the temporal pulsing of the TEGa source during growth. With optimization of the growth conditions, we obtained InGaN nanorods with different In compositions. Images of the InGaN nanorods are shown here. Dislocations are eliminated at the nanorods/template interface. The height of



Figure 4 Demonstration of InGaN nanorods by nano-scale SAG. (a) STEM HAADF of a InGaN nanorod, (c) – (d) The EDXS mapping results of N, Ga, and In, respectively. The InGaN nanorod shows a sharp interface with the GaN nano-buffer. ⁹

dislocation-free InGaN nanorods greatly exceeds (by at least ten times) the critical thickness encountered in conventional heteroepitaxy. Photoluminescence from the InGaN nanorods can be tuned continuously from near ultraviolet (400 nm) to green (~500 nm). Such a breakthrough provides pathway for InGaN nanorods to be used as templates for growing higher In composition light emitting diodes. Our experience in the nano-scale SAG, the lithography techniques, the nano-scale material, optical, and electrical characterization tools will enable us to explore and understand the fundamental science in the microstructure evolution and crystal orientation selection in the nano-SAG.

C. Selective area growth (SAG) of InN

Our group has performed a comprehensive study of InN SAG and lateral growth over micron-size openings on MOCVD GaN. The challenge in the (selective) growth of InN is related to the comparable strength in the In-N covalent bond and the In-In metallic bond. Perfect selectivity and a record lateral overgrowth have been obtained (Figure 5 (a)). The window for successful SAG was delineated and plotted as the green region in Figure 5 (b).



Figure 5 (a) Upper, an inclined SEM image of InN SAG-ELO stripes showing perfect selectivity; lower, a cross-sectional image of InN laterally overgrown on GaN. (b) A phase diagram of InN SAG as a function of temperature and V/III ratio.

At a temperature above roughly 650°C, significant desorption of InN takes place and the surface is populated with In droplets. Below approximately 570°C the pyrolysis of NH3 in MOCVD becomes insufficient and we started to observe either In droplets or a loss of

selectivity (red region). Within the right temperature range, one needs to control the V/III ratio such that In adatoms will have sufficient diffusivity and there is enough supersaturation for nucleation. Our study of InN growth is summarize in Figure 5 (b); We also note that our study of the microscale SAG serves only as a rough map for selectivity and uniform nucleation; the rather narrow window identified in summary plot does not provide enough flexibility in controlling the microstructural evolution. It is revealed in the x-ray diffraction rocking curves of InN prepared by micro-scale SAG has a FWHM of almost 2°. Our preliminary data, as well as those reported by other groups using planar epitaxy, strongly suggest the need to carry out InN SAG using nano-trenches to obtain defect-free samples. Both the geometric effect with small openings, a high-aspect-ratio, and enhanced nanowall interactions, will facilitate a surface-mediated, nanoscale "roller-pressing" of the defective and dispersive InN nuclei to achieve micrometer scale dislocation reduction. Our expertise in the conventional micron-size SAG, particularly in InN SAG will serve general guidelines in carrying out the InN nano-scale selective area growth.

Future Plans

We plan to develop nanolithography technology for patterning high aspect ratio SiO₂ nano-trenches on Si(100), GaN, and textured AlN templates using e-beam lithography and reactive ion dry etching. Selective area growth of InN on the nano-patterned samples will be studied. InN grown in nano-trenches will be characterized using TEM, STM, SEM, EBSD, and micro X-ray diffraction. The effect of geometry confinement, growth condition on microstructural evolution and crystal orientation will be investigated.

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Mesoscale Mechanochemistry of 2D Crystal Growth PI: A. John Hart, Massachusetts Institute of Technology

1. Program Scope

The goal of this program is to investigate the influence of mechanical forces on the nucleation and growth of carbon nanostructures, with specific focus on graphene as a model system for 2D crystal growth. In our original DOE BES program, we developed techniques and instrumentation to study the influence of forces on carbon nanotube (CNT) growth, and since the beginning of the renewal program (September 2014) have we are seeking to study how to manipulate the graphene growth process by application of localized or global forces to the thin film interface (e.g., Ni-graphene-SiO₂). In the past year, we have made two main accomplishments: first, we have nearly completed our work on CNT growth which enabled further refinements to our force-controlled system to begin the new project, and is enabling an integrated understanding of the mesoscale mechanical coupling that influences aligned CNT growth. Therefore, in this abstract, we present work we continued on CNTs while refining our CVD system, and our new work which so far has focused on the design and fabrication of an electrostatic tool for in situ manipulation of graphene growth.

2. Recent Progress

2.1 In situ mechanical manipulation of growing carbon nanotubes (CNTs)

From our previous work, we have revealed that mechanical forces exerted on CNTs as they grow can have a significant impact on the characteristics of vertically aligned CNT forests. To better understand and control the effects of external forces, we have designed and built a custom chemical vapor deposition (CVD) reaction chamber (Fig 1). This system (the 'mechanochamber') can apply a constant force to a CNT forest as it grows inside the chamber while measuring the forest height, using a pushing probe connected in series to a load cell, optical encoder, and voice coil actuator. The system was used to apply static compressive forces throughout growths, ranging from 0.1 to 10g (~1.2 to ~125 kN/m^2 pressure for the 1 mm diameter pillar forest geometry).



Figure 1. (A) Photograph of the custom-built reaction chamber for *in situ* mechanical force application during CVD, with an inset schematic of the critical components. (B) Plot of CNT forest heights throughout the growths for different static compressive loads, and (C) the corresponding average growth rates.

Plots of the forest height vs. time is shown in **Fig. 1.B** Numerical differentiation of these curves reveals the growth kinetics; **Fig 1.C** shows the maximum growth rate for each of the applied loads. It was found that even small increases in applied compressive load results in a

measureable decrease in the growth rate and hastens the onset of growth termination.

Three regimes of force-controlled CNT growth behavior were identified. Low forces (0.1 - 0.6 g) resulted in typical growth and termination behavior. However, the forests grown under moderate forces (0.7 - 4 g) buckled during growth. Even greater forces (5 - 10 g)prevented the CNTs from self-organizing into a forest. These regimes are identified by the growth



Figure 2. (A) Growth kinetics for an experiment performed in each regime: low (blue), moderate (green) and high (orange) applied force. (B-D) SEM images of CNT forests grown in each regime, with insets of higher magnification to show the tortuosity of individual CNTs. (E) Orientation parameters for samples from each regime as obtained by analysis of small-angle X-ray scattering intensity maps.

(height) kinetics curves for the collective forest (**Fig. 2.A**), showing a long period of growth at a high rate followed by rapid termination for low forces (blue), a buckle denoted by a sudden drop in the growth rate followed by growth at a lower rate for moderate forces (green), and immediate decay of a small growth rate for high forces (red). These findings are supported by SEM images of the pillars (**Fig. 2.B-D**), and also by *ex-situ* characterization of the forests by small-angle X-ray scattering (SAXS). Analysis of the scattering data allows the determination of an orientation parameter ranging in value from 1 (vertically aligned) to -0.5 (horizontally aligned), with a value of 0 indicating no directionality. Results for samples from the three regimes (**Fig. 2.E**) show that there may be a slight decrease in vertical alignment of the CNTs between the low and moderate applied forces, but at high force there is a complete loss of vertical alignment and actually a slight horizontal orientation of the CNTs [1]. In addition, we have begun to perform experiments with time-varying forces to investigate the ability of a growing forest to respond to changes in forces, and how the growth rate, morphology, and termination are affected.

2.2 Simulations of growth of mechanically coupled CNTs

Insights on how mesoscale coupling influences CNT growth is enabled by modeling of CNT-CNT interactions along with the dynamic growth process. This work is built on a model that was developed in our group to investigate the strength of CNT yarns that are put in tension [2]. This model creates a three-dimensional representation of CNTs (**Fig. 3.A,B**), determines which CNTs are close enough such that they are within range of van der Waals attractive forces and a contact between them is created, determines the deformation due to van der Waals forces of the CNT cross-section as two CNTs come into contact, finds the strength of the contacts, and adds a growth segment to the bottom of the CNTs proportional in size to their growth rates. Then the geometry of the CNTs in the form of nodes connected by bar elements and contacts in the form of spring elements (**Fig. 3.C**) are used by ANSYS finite element software to displace to the CNTs to simulate growth and determine the resulting stresses. The force measured at the base of each CNT for a simulation of two CNTs of different diameters coming into contact is plotted vs. the mean CNT height in **Fig. 3.D**, with maps of force throughout each CNT at various steps throughout the simulation (**Fig. 3.E**). The smaller CNT is assumed to grow slower than the larger CNT, resulting in the creation of tensile force (red) throughout the smaller CNT and compressive force (blue) throughout the larger CNT once the CNTs come into contact. These simulations show that the mechanical coupling of CNTs of differing growth rates results in dynamic force development and morphological evolution.



Figure 3 (A) Geometric representation of two CNTs coming into contact and (B) the resulting deformed cross sections of the CNTs used as a model. (C) Finite element geometry of two CNTs growing at different rates. (D) Force at the base of each CNT throughout a simulation and (E) force distribution across the CNTs at selected steps of the simulation.

2.3 An electroadhesive tool for in situ mechanical manipulation of graphene

To enable in situ mechanical manipulation of graphene using the mechanically controlled CVD system, we have designed and fabricated an electroadhesive tool that has the capability to control its adhesion force by varying external voltage (**Fig. 4.A**). In addition, the tool is compatible with the harsh growth conditions inside the CVD furnace (i.e. high temperature, reactive gas flow, etc), so it can also be used for in-situ measurement of adhesion force between graphene layers.

The device comprises of conductive electrodes embedded in an insulating layer, such as polymer and ceramic (**Fig. 4.B**). By applying alternative positive and negative charges to adjacent electrodes, electric fields set up opposite charges on the surface of the counterpart material in contact and cause electrostatic attraction between the tool and the counterpart surface [3-5]. The electroadhesion force per area is a function of the square of the applied voltage. Thus, for a preselected tool design, the adhesion force can be controlled by the applied *V*, within the limits imposed by electrical breakdown. A prototype electroadhesive tool has been fabricated on a Si/SiO₂ substrate by conventional lithographic microfabrication methods, involving deposition of TiN in an interdigitated pattern using lift-off process to create the conductive electroadhesion force of the prototyped tool vs. applied voltage is shown in **Figure 4.E**. Initial experiments using this tool to manipulate graphene on substrates with controlled surface chemistry and roughness are being performed.



Figure 4 Schematics showing

(A) the stages of interfacial graphene growth and metal film delamination, (B) the elctrostatic force genereated by electroadhesive tool for in-situ film delamination, and (C) the tool fabrication procedure. (D) Photograph of prototyped electroadhesive tool having TiN as conductive electrodes and SiO₂ as insulating layer, and (E) plot of estimated electrostatic force of the prototype according to the applied voltage.

3. Future Plans

We plan to complete the study of force-modulated growth of CNT forests with additional time-varying compressive force experiments to test the capability of a forest growth to recover from growing under load and to determine the limits of force a growing forest can withstand. This will be combined with additional dynamic modeling, of the coupled forces between CNT pairs and ensembles, to understand how the time-varying forces influence the rate and quality of CNT growth. Combined with insights from TEM experiments that we are also preparing for publication, we will conclude this aspect of the DOE-funded work.

We will then utilize these understandings and the capabilities of our custom equipment to investigate the effects of force on graphene and other 2D material growth. First, we will aim to develop a better understanding of the nucleation and growth of 2D materials by CVD, using graphene as a model example, using *in situ* Raman spectroscopy and optical microscopy techniques. We then hope to investigate the role of mechanical stresses on the growth process, and how they affect diffusion of the reacting species, microstructural evolution of the catalyst film, nucleation and growth energetics, and adhesion energies between the 2D material and the substrate. Our custom CVD chamber with its micromanipulator can also be used in conjunction with the electroadhesion tool we developed in order to investigate the effects of out-of-plane forces on 2D material growth, and to perform *in situ* measurements of adhesion forces

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Characteristic Length Scales of Growing Nanorods

an example of basic science enabled technology

PI: Hanchen Huang, Northeastern University, Boston, MA

Program Scope

Through a combination of analytical formulations, atomistic computer simulations, and physical vapor deposition experiments, the objectives of research are: (1) identification / discovery of the multiple characteristic length scales of growing nanorods, (2) establishment of interdependence of these characteristic length scales and their dependence on growth conditions, and (3) science-based growth of nanorods through the discovery of length scales and gained knowledge of these dependences and important through knowledge integration.

Recent Progress

This report focuses on three relatively more important advancements, leaving out others.

The first category of accomplishment is the development of a theoretical framework of nanorod growth, consisting of two closed-form theories of characteristic length scales [1,2], as shown in Figure 1.

One characteristic length scale is the smallest diameter of metallic nanorods:

 $L_{\min} \approx \left[(10/\alpha^2) \ln (n/2) (v_{3D}/F_e) \right]^{\frac{1}{5}}$ Here, L_{\min} represents the smallest diameter; n is the number of stacked layers that make up the height of the nanorod, which is on the order 1000; α is a geometrical factor where $\alpha = \pi/4$ for circular cross-sections and $\alpha = 1$ for square across-sections; v_{3D} is the diffusion jump rate of adatoms over multiple-layer surface steps; and F_e is the effective deposition rate. This length scale is a new concept, and the closed-form enables clear insight on how it depends on processing conditions and materials properties.



Figure 1: Length scales L_{\min} & L_s vs diffusion $(v_{3D}/F_e)^{\frac{1}{5}}$

The other characteristic length scale is intrinsic separation of metallic nanorods: $L_s = 1.9 \left(\frac{12}{7\pi} \frac{v}{F}\right)^{1/6}$. Here, L_s represents the separation of metallic nanorods; v is the diffusion

jump rate of adatoms over multiple-layer surface steps; and F is the deposition rate. This length

scale is an old concept, but a closed-form never existed. Similarly to the first theory, this also enables clear insight on how it depends on processing conditions and materials properties.

As one demonstration of the impacts of the closed form theories, Figure 1 reveals the phase domains of growth – in the form of either "film" at ultra low diffusion or "nanorod" above a threshold amount of diffusion. This revelation is counterintuitive. In fact, merely one year before these theories were ready, this group published a set of experimental results with the word "anomaly" in the title [3]. Normally, as diffusion is reduced, nanorods of smaller diameter will result. Instead, our own experiments showed that nanorods of smaller diameter did not result but continuous film resulted. This experimental observation was an anomaly according to the understanding at the time. With the two closed forms theories, as shown in Figure 1, this "anomaly" now is predicted and should be considered "normal"!

The second category of accomplishment is the experimental realization of the smallest wellseparated metallic nanorods [1].

In nano materials research, being able to grow smaller structures can mean advancement. However, claiming the growth of the smallest structure can easily cause an uproar.

Luckily, for us the smallest diameter of nanorods is predicted by a closed-form theory. Further, the other closed-form theory also reveals how the separation of nanorods varies. Guided by the theoretical framework, we have successfully achieved the smallest wellseparated metallic nanorods. Figure 2 shows that the smallest Cu nanorods are on the order of 25 nm in diameter; this number becomes about 7 nm for Au.



Figure 2: SEM image of Cu nanorods

The third category of accomplishment is in the form of a patented technology – metallic glue in ambient [4,5].

Taking advantage of the "smallest" and "well-separated" nature of the metallic nanorods, as shown in Figure 2, we now have proposed and achieved metallic glue in ambient – at room temperature, in air, and under small pressure of a few megapascals. To glue two solids, we coat each with metallic nanorods and push the two solids together with nanorods facing each other. The well-separated nature allows nanorods to easily interpenetrate, and the small dimension promotes fast surface diffusion. As a result, the two sets of nanorods sinter to form continuous metallic glue. Such metallic glues have many advantages. For example, their leak resistance (to

air or moisture) is at least 1000X better than that of polymer glue, so their use in organic solar cells would meet the US DoE standard of leak resistance. As another example, because the metallic glue forms at room temperature, they can take the place of solder for printed-circuit-board connections in integrated circuits with minimal thermal budget.

This technology development is an example of how BES research can lead to technologies that are directly relevant to DoE missions.

Future Plans

A major effort will be in the generalization of the nanorod growth theory. So far, we have formulated the smallest diameter of nanorod. On the other extreme, there are characteristic length scales of epitaxial thin film growth – such as the dimension of mounds according to the wedding cake model. In the extreme of growing the smallest metallic nanorods, multiple-layer surface steps dominate; in the extreme of epitaxial thin film growth, monolayer surface steps dominate. In between the two extremes, monolayer and multiple-layer surface steps both affect the growth, and the dynamics of conversion between monolayer and multiple-layer surface steps will be the key in the generalized theory of growth, which applies for both nanorod growth and thin film growth.

Like in the past, we will continue to design nanorods in parallel with the theoretical development and will continue to use the combination of analytical formulations, atomistic computer simulations, and physical vapor deposition experiments in our studies.

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Laser fabrication of single-crystal architecture in glass: control of morphology

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Program Scope

Numerous energy devices and technologies rely on the availability of suitable single crystals of complex compositions in appropriate form. The conventional thermal processes for fabricating single crystals from the melt are not suitable for many important multi-component systems because either the material decomposes before melting, or undesired phases form by incongruent solidification of the melt. We are addressing this generic challenge of material fabrication by attempting to grow a single crystal architecture by heating glass to peak crystallization temperature with a suitable laser without melting. The project focuses on developing an understanding of the laser-crystallization process that will allow the control of size, geometry and orientation of the laser-written single crystal, specifically enabling the fabrication of a bend in the single-crystal line and then a 2D planar single crystal, without altering the orientation of the lattice.

Our approach is based on two hypotheses: (i) The key element for the desired control of the crystal growth is the *dynamic temperature profile which determines rate-controlling local diffusivities and interfacial reaction kinetics.* (ii) A laser can help realize complex heating profiles that are not possible with any other technique. Consequently, we are determining the heat profile and the dependence of growth on local (anisotropic) temperature gradient. With this information appropriate dynamic temperature profile are being established, which would yield specified crystal geometry (shape and size) in a given glass. High resolution spatial light modulator technology, which has become readily available only recently, is to be used to shape precisely and vary dynamically essentially arbitrary beam profiles. The initial crystal growth experiments are to be performed on IR transmitting Sb-Se, Ge-Se and Sb-S/Se-I chalcogenide systems comprised of active crystal phases that have unusual combination of superior piezoelectric, pyroelectric and pyro-optic properties. These systems allow a systematic variation of network dimensionality, hence growth anisotropy. Successful understanding of single crystal growth process in these compositions would help establish its broad applicability to various other glass forming systems.

Recent Progress

Fabrication of single crystal architecture in glass requires slow nucleation and rapid crystal growth rates such that once a nucleus is formed only one single crystal grows. Unlike classical glass-ceramic process, laser heating largely precludes nucleation except in the immediate vicinity of localized heated zone. Even then, unlike for the case of usual crystal growth from the melt or solution, these requirements become particularly challenging for the case of glass \rightarrow single-crystal transformation where formation of multiple crystals is thermodynamically feasible.

<u>1. All solid-state single crystal growth:</u> At first, crystal dots were formed on surface of Sb_2S_3 glass by a 639 nm CW laser. Fig. 1 shows an image sequence of the nucleation and growth of the Sb_2S_3 single crystal on the surface of glass of the same chemical composition. The growth of Sb_2S_3 crystal after a few seconds is very fast (~10-15 µm/s). Electron backscattered diffraction (EBSD) mapping shows that only one nucleus was introduced that grows at the glass surface (Fig. 1(b-e)). The nucleus which appears at the glass surface grows very rapidly and does not give chance for other nuclei to form and grow. Furthermore, the nucleation of Sb_2S_3 crystals on stoichiometric glass is significantly faster than on $16SbI_3$ -84Sb₂S₃ glass, confirming that glass composition can be manipulated for avoiding the formation of multiple nuclei and thereby enhancing the chance of single crystal fabrication.

The results demonstrate for the first time the possibility of growing single crystal from glass exclusively by solid-state transformation. There are two independent key observations, which prove that the glass→single crystal transformation occurs entirely in the solid state. First, scratches that were present on the glass surface before laser irradiation (most clearly in the region of the lines - see arrows in Fig. 2(a)) persist through the crystallization process, indicating that the nucleation



persist through the crystallization process, indicating that the nucleation and growth processes occur without forming a melt that would have altered the surface morphology. Second, the in situ observation of the crystal growth process demonstrates that the

morphology. Second, the in situ observation of the crystal growth process demonstrates that the crystallization occurs at the leading, not the trailing edge of the laser beam. This mode of crystal growth provides a proof-of-concept for fabricating single crystals of complex materials that melt incongruently, decompose or undergo phase transformation during heating to melt temperature.

2. Crystal growth with rotatory lattice orientation: EBSD mapping indicates that the laser-crystallized line starting from a single dot is essentially a single crystal. However, a more careful analysis revealed gradual, but continuous rotation of the lattice about a direction parallel to glass surface but normal to laser scanning direction, e.g. for Sb₂S₃ glass the crystal rotates by $\sim 50^{\circ}$ over a length of 100 µm. Fig. 2 shows maps for three orthogonal EBSD reference directions of such a crystal line. There is no change in the orientation of lattice perpendicular to laser scanning direction (TD, Fig. 2, d), but a gradual change of color (orientation) from the start to the end of the line for the other two orthogonal directions (Fig. 2b, c).

The X-ray microdiffraction at Lawrence Berkeley National Laboratory (LBNL) probed the orientation of crystal up to 100 μ m deep. Laue images, obtained from line, comprise of split

reflex spots with rod-like intensity distribution, similar to the reflections observed for plastically deformed pure metal single crystals. The laser-grown Sb₂S₃ single crystal appears as if it is "plastically deformed", with unpaired dislocations and small-angle tilt crystal boundaries. The growing accommodates its structural mismatch with glass matrix by introducing such dislocations, which might even organize to form tilt dislocation walls, but that remains to be determined. These dislocations cause rotation along the direction of growth, which coincides with the laser scanning direction.

3. Growth of 2D single crystal layer: To fabricate 2D single crystal, first a single crystal line was formed for use as the initial nucleation site for subsequent single crystal lines formed by rastering the laser beam perpendicular to this line. A 2D single-crystal pattern was obtained by 'stitching' successive lines. А successful example of this methodology is shown in Fig. 3 where each line was 50 µm long (horizontal in the figure) and shifted by 10 µm from the preceding line in the vertical direction. As above, the colored crystal orientation deviation (COD) map of the 2D pattern



Fig. 2. The laser-written crystal line on the surface of Sb_2S_3 glass. Scale bar corresponds to 5 μ m. (a) SEM image and colored orientation IPF maps with reference vector in the direction of (b) surface normal ND, (c) scanning direction (SD), and (d) transverse direction (TD). The local lattice orientation as determined on selected points on the IPF RD map (c) shows rotation of lattice.

shows gradual but small color change only between the lines in vertical direction ($<0.1^0/\mu m$); there is virtually no rotation along the lines (horizontal direction in the figure).

In conclusion, we: (1) demonstrated for the first time the feasibility of all-solid-state single crystal growth from glass; (2) discovered a gradual rotation of lattice laser-written single-crystals to accommodate density mismatch by incorporating unpaired dislocations in the structure; and (3) demonstrated the fabrication of 2D single crystal architecture as well as bent single-crystal lines.

Future Plans

<u>1. Correlation between laser beam profile and single crystal growth.</u> The main focus of the project in the next period will be on establishing the impact of laser beam profile, hence the local temperature profile, on the nucleation and growth of single crystal. The usual Gaussian intensity profile of the laser

beam from a diode has proven already to be problematic for single crystal growth. For example, the high intensity in the center of beams typical causes evaporation while the crystal grows at the periphery, as in Fig.1. To overcome such problems and develop a general understanding of the role of beam profile in laser



crystallization, we will manipulate beam profile with a spatial light modulator (SLM) to create desired intensity patterns on the sample. We have observed that often the laser-induced crystal nuclei of Sb_2S_3 exhibit preferred orientation when formed in glass matrix. We propose to investigate and establish correlation between the beam profile and crystal orientation systematically, by controlling the intensity and shape of laser beam during nucleation using SLM.

2. Characterization and control of lattice rotation during crystal growth. As noted above, the lattice of single crystal line formed on the surface of glass undergoes gradual rotation to accommodate the density mismatch between the glass and crystal. However, the magnitude of this rotation ($^{\circ}/\mu$ m) varies significantly with the orientation of crystal line relative to laser scanning direction. In fact, for some specific direction this rotation may not occur at all. We will continue investigating the mechanism of oriented nucleation and 'rotating' growth of Sb₂S₃ crystals, by characterizing the nature of interface between the crystalline and the surrounding glass phases, difference in their short-range order as well as stress and dislocation distribution generated by density/structure mismatch. Potentially useful techniques for our purpose are: X-ray fluorescence imaging and EXAFS spectroscopy as well as X-ray microdiffraction, which will be performed with the required sub-100nm spatial resolution at National Synchrotron Light Source II, Brookhaven National Laboratory and at Advanced Light Source, LBNL, respectively.

<u>3. Fabrication of 2D crystal.</u> Having demonstrated the initial feasibility of 2D single crystal on the surface of glass, we will continue with the optimization of the fabrication process, in particular the 'stitching' of single crystal lines that have rotating lattice. It will require an understanding of how lattice orientations are adjusted during laser growth process, such as seen in Fig. 3. The results obtained from the experiments described above will guide the fabrication of macroscopic 2D crystals.

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Synthesis and Processing Research in Group IV Nanomembranes

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Program Scope

Single-crystal semiconductor sheets present a platform for entirely new science and technology. They may form the basis for devices relevant in energy harvesting, transformation, and conservation. The novelty of thin crystalline sheets lies in the following. 1) They are **thin**; a factor that brings many new phenomena. The very high interface-to-volume ratio makes surfaces or interfaces, and their chemical and structural properties, very important contributors to unique membrane electrical, thermal, photonic, and mechanical behavior. 2) Thin sheets can be **strained** to a high degree, effectively allowing lattice constant choice over a significant range. Most fundamental materials properties are influenced by the lattice and distortions of the lattice. 3) Thin sheets are easily **stackable** and **bondable**, introducing the potential for an entirely new set of composite materials that change their properties vertically on the scale of 10s to 100s of nm. Because of this property, **interface effects** can be significant. Additionally and importantly, sheets are compatible with all top-down processing that is conventional in the semiconductor device industry, and thus provide ready potential for technological application.

Our work has focused on the development and use of Group-IV-element and alloy nanomembranes, The platform is extendable to other materials and a range of structures and functions, using the materials processing approaches we have developed. The platform of single-crystal semiconductor sheets offers the true advantage of working at the nanoscale in one dimension, while the other two dimensions are at the mesoscale or macroscale. Our work provides excellent prospects for modifying and enhancing materials properties, and new areas of NM processing that can act as technology drivers.

The program scope is broad and includes:

- Investigations of
 - electronic transport in surfaces of crystalline sheets (primarily Si and Ge of different orientations), including graphene bonded to such NMs and two-dimensional electron gases
 - strain engineering of new structures, including local and global lattice strain, externally applied strain, and thermal mismatch strain
 - novel interfaces, including structure and thermal/electrical transport through NM stacks and periodically rippled NMs
 - surface or materials modification to affect the kinetic barriers for defect formation during stress application
- Fabrication of our own unique NMs, make novel materials via NM strain engineering
- Application of theory to quantify the outcomes of our synthesis and processing efforts
- Focus on structure and defects, electronic band structure, electronic and thermal transport, and mechanical behavior.

Recent Progress

We are actively investigating a number of research topics at the forefront of semiconductor (and to a slight degree oxide) NM science. Our core competencies are making NMs via thinning, release, etching and transfer, using MBE and CVD growth at very high purities; charge transport measurements in very thin sheets; structural and strain measurements; surface characterization, and investigation of fundamental mechanisms of growth. We have focused in the last two years on

- Use of strain engineering to make defect free Si-Ge crystals and their use for multiplequantum well growth of Si/SiGe heterostructures and strained-Si 2DEGs
- Exploration of the properties of strained-Si quantum wells related to interface roughness, growth, impurities, and extended defects
- Mechanical strain of Ge for band engineering, including now the formation and straining of P/graphene/N junctions
- Charge transport in graphene grown on or transferred to semiconductors; influence of interface; measurements of lateral conduction
- Thermal transport through stacked-NM interfaces, so far SiNMs, but other variants in progress.
- Surface charge transport in Si(001) using a gated van der Pauw technique. Now attempting to do Si(111). NMs attached to oxide (as a gate dielectric) are required for this work
- Initial efforts on improving the quality of oxide NMs by annealing thin sheets
- Use of free-standing SiNM as a strain gauge to investigate thin-film stress evolution during growth

We describe here examples of the above bullets. Of considerable recent interest is the work on charge transport in graphene transferred to Ge(001).¹ The excellent conductivity and high charge carrier mobility of graphene suggests several applications in fast analog electronics, including transistors potentially operating in the THz regime, as well as graphene electrodes to replace indium tin oxide and graphene interconnects with low resistance and capacitance to replace copper. These applications do not require a band gap. The realization of any graphene-based device is dependent, however, on finding functional substrates on which the high carrier mobility observed for freestanding sheets of graphene is maintained. Transfer to the several materials that have been tested as hosts has always led to a degradation of this mobility. In contrast, when we transfer graphene to Ge(001), its conductivity is extremely high and remains high over time: the mobility is higher than for freestanding graphene and the carrier density is also very high. We have determined that the suboxide of Ge, which is very difficult to remove with conventional methods, provides the charges and thus effectively dopes the graphene. We explain the results with a metal-semiconductor junction model of this complex interface.

Corresponding measurements on graphene grown (rather than transferred) to Ge do not show the high conductivity. In such samples, the Ge oxide disappears because the growth process occurs at high temperatures. The removal of the oxide apparently eliminates the source of dopant charges for the graphene. On the other hand, graphene grown on Ge effectively passivates Ge from oxidation,² a fact that provides encouraging potential for future use of Ge in semiconductor devices. This research began as a serendipity result that is expanding rapidly, with potentially major consequences.

Free-standing SiNMs, tethered only at their perimeter to a host, represent a uniform canvas on which one can deposit materials and indirectly observe their growth and the resulting stress evolution and nanoparticle distribution on a highly localized (sub-micron) scale by mapping the imparted stress from the adsorbate to the NM using Raman spectroscopy. The thin single crystal-line Si (or other semiconductor) nanomembrane serves as a strain gauge, where the film stress can be inferred from the required balance of forces in the film/NM system. The reliability of microelectronic and micro-electromechanical systems is limited by stress induced failure mechanisms. Most defects are caused by local stresses, requiring development of local probes that could dynamically measure film stress evolution during growth, or post processing. We performed preliminary measurements of this sort,³ that were not entirely successful because we did the experiment incorrectly, but we learned how to do them correctly. We have demonstrated the fabrication of tethered NMs for this purpose, and analyzed the average strain evolution of amorphous SiN films.

In a thin semiconductor sheet, the simple existence of surfaces can have significant impact on the "bulk" conductance of the sheet by providing states, via a mechanism called "surface transfer doping". But the surface may itself conduct, independent of the bulk, through extended electronic states at the surface, an important function in many current nanostructure investigations that is quite difficult to measure. We use an electrode at the back of the wafer ("back gate") to deplete the "bulk" of the thin Si layer, revealing the non-zero conductivity in the surface bands, caused by the 2x1 reconstruction of the clean surface. A change in NM thickness modifies the coupling strength between the front free surface and the back gate. Any changes in the front surface then act as an additional gate to counter or enhance the effect of the back gate. The NM "bulk" conductance is continuously tunable by the back gate voltage and hence can be made negligible relative to the surface contribution.

We are continuing conductance measurements in UHV on thin SiNMs, but now on Si(111). From the shape of conductance plots as a function of back gate voltage, we can determine electron transport through potential surface bands separately from the bulk conduction. The reason for investigating Si(111) is to resolve a controversy whether the surface is metallic or semiconducting. We have had difficulties because SOI(111) is not readily commercially available and is mostly of very poor quality, with leakage through the oxide. We hope to resolve this problem by careful selection and presorting of the material. We have similar problems with availability of GOI (for Ge NMs), and have begun to make our own, using III-V templates and Ge OMVPE. We use – and plan to use – GeNMs for a wide variety of applications, because we can make Ge direct-bandgap by applying biaxial tensile stress of sufficient magnitude.⁴

We have now been successful in measurements of thermal transport through interfaces created by NMs stacked on top of a substrate or each other.⁵ Thermal transport and management is a critical issue for semiconductors with structural interfaces. In applications in thermoelectrics, high thermal resistance is desired, while in other applications low thermal resistance is of benefit in dissipating heat from hotspots. We show that the thermal resistance across a Si/SiNM stack can be very low and is highly dependent on the nature of the surface preparation prior to assembly. Here, the inclusion of an oxide layer at the interface reduces the thermal resistivity beyond a simple clean H-terminated surface; a feature attributed to increased interfacial binding energy in the former case. The development of electronics based on stacked systems of both identical and dissimilar materials renders the question of thermal transport across different interfaces increasingly important. We will therefore continue such experiments.

Future Plans

We are in the last half year of this grant. Rather than attempt to define here what we plan to propose in a renewal grant, we will simply say here that the most interesting parts of the above projects will be continued. Work on combining graphene and Ge will continue. Mechanically straining Ge to investigate optoelectronic and light emission effects will continue (e.g., possibly improved light emitting diodes). Thermal transport measurements will be expanded to multiple interfaces and different NMs and combinations, including graphene. For both the surface transport and the SiGe NM substrate and growth studies, we will continue to fabricate step-free mesas. For surface transport this is important because we can eliminate steps and thus dimer row orientation as causes for limited surface mobility. For the growth studies it is important because steps influence the behavior of a strained-Si 2DEG. Several other projects will continue.

The effort on hard/soft materials combinations will be ended or scaled back, not for lack of success, but because they were primarily the work of a postdoc, Francesca Cavallo, who now has a faculty position at the University of New Mexico, and is successfully continuing the work there. We do not want to compete with our own offspring.

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Quasiepitaxial Growth of Organic Crystalline Thin-Films

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Program Scope:

The presence of excitons in organic semiconductors at room temperature distinguish them from traditional semiconductors, providing exceptional opportunities for manipulating energy in a range of structures from light emitting diodes, lasers, transparent photovoltaics, and optical switches, and have already shown superior performance in the light emitting diode (LED) field. However, control over crystalline order, orientation, and defect formation are crucial to the fabrication and optimization of these excitonic organic electronics. For organic growth, lattice matching is not strictly required as with inorganic epitaxy, and the modes of epitaxy are therefore uniquely distinct. For example, unmistakable azimuthal relationships have been observed for many organic molecules grown on inorganic crystals that are consistent with theoretical energetic minima, despite a lack of true commensurate "epitaxial" relationship (hence the term "quasi-epitaxy"). While there is a growing body of literature on organic quasiepitaxy (QE) on inorganic substrates, very little is known about organic-organic QE needed to push excitonic electronics to their full potential.¹ Indeed, very little is even known about homo-epitaxial vaporphase growth. This is due, in large part, to 1) a lack of high quality starting crystalline organic layers, 2) limited implementation of real-time probing methods and 3) a lack of understanding governing organic-organic QE selection rules. Moreover, there have been few examples of preserved-ordering during multilayer crystalline organic growth despite the keen interest in the novel physics afforded by crystalline organic semiconductors. Accordingly, there is a wealth of opportunities for this unexplored regime of organic crystalline growth phenomena. The overarching goal of this project is to understand and explore bottom-up vapor-deposition routes to the growth of large-area organic crystalline films with controlled thickness, doping, and defect concentration.

Recent Progress

We have realized the growth of the first *set* of heteroquasiepitaxial multilayer organic thin film crystals with unprecedented ordering and demonstrated an entirely new growth mode in organic-organic quasiepitaxy. We have grown crystals composed of incommensurate organic semiconductors with sustained azimuthal ordering and controlled orientation grown from the bottom up. By probing a range of molecular pairings with *in-situ* and *real-time* diffraction, we are uncovering the key driving forces behind this underexplored growth regime that derives from interactions which are completely distinct from the requirements of lattice matching for inorganic epitaxial growth. We subsequently focus on the quasiepitaxial growth of a range of key organic molecules including diinendenoperylene (important in thin film transistors and light emitting diodes), rubrene (high mobility transistors, light emitting diodes, and photovoltaics), perylenes, and phthalocyanines (important in photovoltaic applications), among others.

A) Uncovering a New Growth Mode: Edge-Driven Organic-on-Organic Quasiepitaxy

We have demonstrated an entirely new growth mode and unique ordering of alternating hetero-quasiepitaxy of 1,4,5,8-naphthalenetetracarboxylic-dianhydride (NTCDA) and diindenoperylene (DIP) crystalline films. Despite matching of the lowest energy surfaces (LES) between the two systems, DIP orients on NTCDA by exposing the β -DIP(020) surface, a non-lowest energy plane. Calculations of potential energy for the two-layer stacking model are performed to understand the quasiepitaxial relationship and highlight the complex dynamics of this new quasiepitaxial growth mode, driven not by surface energy landscape, but by organic-organic step-edge nucleation interactions. Understanding this new growth mode ultimately provides a novel mechanism to highly ordered organic quantum wells with tailored orientation and anisotropy that can enhance excitonic electronic devices, and provides an intriguing counterpoint to the understanding of organic multilayer epitaxy.

A typical series of reflection high energy electron diffraction (RHEED) patterns for the growth of NTCDA/DIP alternating layer structures grown at room temperature are shown in Fig. 1. Although there is no lattice matching between layers, RHEED patterns reveal that each layer is highly crystalline with its own well-defined surface lattice and registry. When NTCDA is grown on the KBr substrate, the RHEED patterns show continuous streak features, indicative of crystalline flat surface that is consistent with the two-dimensional growth. With the subsequent growth of the DIP layer at room temperature, long unbroken NTCDA diffraction streaks are replaced by spotty diffraction patterns of DIP which indicates a roughening of the crystalline surface. Nonetheless, clear azimuthal registry is still observed and the single-crystal-like rotational dependence of the RHEED patterns indicates that the DIP grains are all aligned in-plane on top of the NTCDA layer. Despite the fact that β -DIP(001) is the LES and has a close energy matching with NTCDA(100), the β -DIP(020) plane is formed on the NTCDA surface, which is confirmed by both RHEED and XRD data. This multilayer growth was repeated for a number of cycles and clearly demonstrates the ability to grow incommensurate organic



Figure 1. RHEED patterns of the (a) the initial substrate and (b-c) the first, (d-e) second, and (f-g) third pair growth of NTCDA(10nm)/DIP(10nm) multilayers. (h-m) with representative AFM image for each molecular film included. (inset) Structures of the KBr substrate and molecular structures of NTCDA and DIP.

films, layer after layer, with sustained azimuthal ordering and controlled orientation, reminiscent of molecular beam epitaxy of inorganic quantum wells.

This surprising growth configuration is shown to be driven by edge-nucleation driven

quasiepitaxial dynamics confirmed by in situ diffraction, equilibrium energetic predictions, growth order reversal, and early growth studies. For example, growths were performed with reverse layer sequence, starting with the DIP layer first. Interestingly, the spotty RHEED patterns in Fig. 2 no longer align orthogonally to the surface plane, indicating the formation of DIP with an entirely different stacking orientation. AFM shows the formation of long nanowire features also distinct from the growth on NTCDA. Subsequent growth of NTCDA on DIP/KBr results in ring diffraction patterns which indicates the evolution of three dimensional crystalline disorder (i.e. crystalline powder) after just the first layer pair. Thus, the initial presence of the NTCDA is key to enable highly ordered multilayer growth. An important



Figure 2. RHEED patterns of DIP/NTCDA starting with DIP first. (a) The pattern for DIP on KBr is distinct to the pattern for DIP grown on NTCDA indicating a significantly altered molecular stacking orientation. Subsequent growth of NTCDA leads to a 3D disordered powder.

distinguishing factor in this pairing is that DIP has a perylene core capable of near covalent-like bonding to other aromatic rings, metals,^{2, 3}, and can support hydrogen bonding interactions,⁴ which has been previously seen in pervlene tetracarboxylic dianhydride (PTCDA) and exploited for molecular templating.⁵ This can create stronger interactions between the DIP molecule and the flat facing edge of the NTCDA step and indeed is consistent with the clear tendency of DIP to nucleate from the step edges of the NTCDA seen in early growth AFM (Fig. 3). In contrast with this picture, we have found that many common organic molecules, including tetracene, coronene, CuPc and C₆₀, grow without a preferential nucleation at edges (intra-terrace nucleation) on NTCDA. Additionally, despite growths with coverage of 1 ML (and a uniform deposition coverage observed concurrently for DIP on SiO_2) we do not find DIP nuclei uniformly distributed on every terrace, and find particularly few DIP nuclei on the largest terraces indicating that there is both a small Ehrlich–Schwöebel barrier⁶ for DIP molecules to reach different terraces and there is a high diffusivity for DIP on NTCDA. This high diffusivity also likely plays a role in the ability to observe this growth mode, similarly to the role diffusivity plays in the transition between layer-by-layer (intra terrace nucleation) and step flow (step edge nucleation) growth in homoepitaxial inorganic systems.



Figure 3. (left) AFM images of subonolayer growth of DIP (< 1nm) on NTCDA. The DIP nuclei are marked with the black arrows. The white scale bar corresponds $0.2\mu m$. (right) Schematic structural model of the NTCDA terraces and edge nucleation of DIP, highlighting the molecular core interactions(shown in blue)

Ultimately, understanding this non-equilibrium quasiepitaxial growth of crystalline organic multilayers will provide new routes to controlling molecular orientation in organic quantum wells via control over nucleation dynamics through the rational design of step-edge molecule interactions, and therefore can enable pathways to enhanced excitonic devices and novel exciton confinement photophysics.

B) Matched Multilayer Growth: NTCDA and Rubrene

We have grown a full range of key molecules on NTCDA to explore the impact of surface energy matching, including metal phthalocyanines, tetracene, pentacene, rubrene, C₆₀, coronene, p-6p, and sexithiophene, and found well-defined ordering only in specific cases. Through close surface energy matching of the lowest energy planes, we demonstrate growth of rubrene that is not only crystalline, but also quasiepitaxial ordered. Rubrene is a particularly important organic molecule as mobilities (> $10 \text{cm}^2/\text{V-s}$) have been demonstrated in bulk single crystals. However, the ability to utilize thin films of rubrene with high performance has been long-standing challenge since the growth of crystalline films is notoriously difficult and commonly yields amorphous layers. As shown in Figure 3, rubrene grows in highly ordered films on the NTCDA layer forming clearly defined streaks with a distinct and incommensurate lattice, providing another platform to characterize carrier transport with tailored crystal structures for highly ordered organic electronic systems.



Figure 4. RHEED patterns of the substrate and the NTCDA/rubrene multilayer growth.

Future Plans

We plan to fully explore homoepitaxial and heteroquasiepitaxial growth modes for the complete representative range of key archetypal organic semiconductors, (2) correlate growth mode with dynamic parameters such as surface diffusivity and growth conditions; (3) correlate optical and electrical properties of highly ordered single- and multi-layer crystalline films via transistor, quantum well (optical), and exciton diffusion length measurements; (4) demonstrate phosphorescent doping during homo- and quasi-epitaxial growth; and (5) exploit this ability to grow highly ordered films to enhance the performance of excitonic devices.

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Non-equilibrium effects in the processing of materials using plasmas

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Program Scope

In the last few years, it has become obvious that non-thermal plasmas are an excellent route for the synthesis and processing of free-standing silicon nanoparticles. Silicon nanoparticles have many interesting properties and relevant applications [1], and have been successfully integrated in nanoelectronics [2], light emitting devices [3, 4] and photovoltaic devices [5]. Nanostructures based on silicon are potentially compatible with large-scale applications, since silicon is the second most abundant element on Earth. Silicon nanoparticles have successfully been produced using non-thermal plasma reactors deliberately optimized for the production of nanoparticles [6, 7]. Non-thermal plasma continuous flow reactors convert silane into silicon nanocrystals sufficiently small to show quantum confinement effects [8]. Despite the fact that plasma-based techniques are promising candidates for the large volume synthesis of silicon nanocrystals, a detailed understanding of the correlation between plasma properties and nanoparticle structure is missing. The question remains of how the continuous flow reactor introduced in [6] fully converts the silane precursor into particles with a crystalline structure within few milliseconds. The goal of this program is to address this open issue and to investigate the interaction between non-thermal plasmas and silicon nanoparticles dispersed within it, with the goal of understanding the influence of plasma parameters of nanoparticle properties such as surface passivation and structure.

Recent Progress

We have pursued two different approaches to establish a correlation between plasma and nanoparticle properties. In the first approach, we have used the kinetics of nucleation, growth and crystallization of nanoparticles in plasma to estimate the temperature to which nanoparticles are heated to when immersed in a non-thermal plasma. In the second approach, we have monitored the evolution of nanoparticle surface coverage during plasma exposure to obtain a nanoparticle temperature measurement.

The first approach [9] is based on the sampling of nanoparticles during different stages of the growth process. Figure 1a is a photograph of the reactor used for that purpose. Nanoparticles are aerodynamically extracted from the plasma volume and collected onto a substrate for *ex-situ* characterization (XRD, TEM, Raman). *In-situ* FTIR is also used to monitor the consumption of the precursor (silane) as the nanoparticles nucleate and grow. Figure 1b summarizes the findings: silane is consumed and converted into nanoparticles on a time scale of 50 milliseconds. This time scale is determined using the gas flow velocity through the reactor and the distance over which the silane signal is no longer detectable. At the end of the nucleation process the nanoparticles

have a size of 5-10 nm with an amorphous structure, as determined by TEM and Raman. At this point the nanoparticles are immersed into an argon-hydrogen plasma, with the hydrogen being the result of the silane decomposition process. The structure of the particles evolves from amorphous to crystalline on a time scale of 100-150 milliseconds, as determined by the distance over which the particles go from a fully amorphous structure to a crystalline one. This direct measurement of the time scale over which crystallization occurs allows determining the nanoparticle temperature during this process, under the assumption that the non-thermal plasma effectively behaves as an "annealing furnace", and once the crystallization rate of the particles is known. Regarding this first point, there are several theoretical contributions predicting that reactions occurring at the nanoparticle surface (H-atom and argon ion recombination) lead to substantial heating [10, 11]. Regarding the second point, we have performed an independent measurement of the nanoparticle crystallization rate by producing amorphous silicon particles and by annealing them in-flight through a tube furnace [12]. By using this experimentally determined



Figure 1. (a) Photograph of reactor for the aerodynamic extraction of nanoparticles at different stages of growth. (b) Summary of precursor consumption, particle diameter and particle structure along reactor length.

crystallization rate, and by using the 150 millisecond crystallization time measured using the approach described above, we have determined that the particles must be heated to a temperature of at least 1100K while in the non-thermal plasma.

The second approach is based on the monitoring of the nanoparticle surface while exposed to the non-thermal plasma [13]. We have used the reactor shown in figure 2 to (a) produce silicon particles in a first plasma and then (b) pass them through a second plasma where they are treated at different input powers. An IR beam is passed through the second plasma, and the Si-H surface coverage is monitored as a function of input power in the second plasma. In figure 3 we plot the integral absorption from the SiH_x stretching modes centered around 2100 cm⁻¹ vs. input power. We find that the surface coverage decreases as the plasma power is increased, and that the hydride moieties are effectively removed from the particle surface for an input power of 60W. We compare these results to simple theoretical calculation based on the kinetics of hydrogen desorption from flat silicon surfaces exposed to a hydrogen-containing

plasma. The flux of atomic hydrogen to the silicon surface maintains the coverage to near 100% up to 600-700K, when thermal desorption leads to a decrease in hydrogen surface coverage. We should stress that we have performed careful control experiments to account for the contribution from UV exposure and ion bombardment to the hydrogen desorption kinetics. We have collected nanoparticles onto a stainless steel mesh placed in the center of the second plasma, and exposed them to the discharge



Figure 2. Photograph of reactor for the *in-situ* characterization of nanoparticle surface as a function of plasma input power.

at different power levels while monitoring the signal from SiH_x species. We have found that even with a 1 second exposure to the plasma (compared to the ~100 millisecond residence time for the in-flight exposure case) there is only a minimal loss of surface hydride species. The difference between the supported case (particles onto a stainless steel mesh) and the in-flight case (particle free-standing in the gas stream) is that in the second case are effectively thermally insulated and become sufficiently hot to desorb the surface hydrogen.

The results from these two different techniques are consistent with each other. When using the crystallization rate to determine the nanoparticle temperature, we obtain a temperature excess compared to the gas temperature (which is safely assumed to be 300K for a non-thermal plasma) of 800K for a power density of 0.8 W/cm³, which is calculated using the electrical power input to the discharge and the plasma volume. When using desorption of hydrogen from the particle surface as a temperature probe, we obtain 400K for a density of 0.5 W/cm³, indicating that the two techniques are in reasonably good agreement.



Figure 3. Nanoparticle surface coverage with SiH_x groups as a function of plasma power.

Future Plans

The studies outline above confirm that non-thermal plasma induce significant nanoparticle heating despite the fact that the gas temperature is near to room temperature. This has important implications from the materials processing point of view. Our future efforts will focus on exploring the consequences of non-equilibrium processing conditions not only on nanoparticle structure but on the surface chemistry of the nanopowder as well. We will in particular explore the mechanisms enabling the in-flight plasma-induced surface modification of particles.

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- Yasar-Inceoglu, O., L. Zhong, and L. Mangolini, *Core/shell silicon/polyaniline particles via in-flight plasma-induced polymerization*. Journal of Physics D: Applied Physics, 2015. 48(31): p. 314009.
- 3. Coleman, D., et al., *Hollow silicon carbide nanoparticles from a non-thermal plasma process.* Journal of Applied Physics, 2015. **117**(19): p. 193301.
- 4. Lopez, T. and L. Mangolini, *On the nucleation and crystallization of nanoparticles in continuous-flow nonthermal plasma reactors.* Journal of Vacuum Science & amp; Technology B, 2014. **32**(6): p. 061802.
- 5. Lopez, T. and L. Mangolini, *Low activation energy for the crystallization of amorphous silicon nanoparticles*. Nanoscale, 2014. **6**(3): p. 1286-1294.
Novel exotic properties of two-dimensional atomic crystals of layered ternary transition metal chalcogenides

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Program Scope

Individual atomically-thin layer of transition metal dichalcogenides (TMDCs) such as MoS_2 and WS_2 has recently attracted enormous interest [1-3]. Their distinct properties, such as large direct band gaps and high photoresponsibility, have tremendous potential for applications in nanoelectronics and optoelectronics. Given the fascinating properties of 2D binary TMDCs, the PIs are particularly interested in studying whether 2D atomically-thin semiconductors can be realized in layered ternary transition metal chalcogenides (TTMCs). The distinct properties of 2D TMDCs are attributed to the combined effects of quantum confinement, localized *d*-bands, spin-orbital coupling (SOC), and inversion symmetry breaking. In layered TTMCs, some of these parameters can have greater tunability. Including a 3d-element in a TTMC can enhance Van Hove singularities in the density of states, which likely results in a remarkable enhancement to the electric field effect and optical absorption. 3d ions such as Fe and Mn can also carry magnetic moments and possibly lead to coexistence of semiconductivity and magnetism. Including a heavy element such as a 4d/5d-element or Sb/Bi in a TTMC would bring in strong SOC, which, when combined with strong electron correlation, may create emergent properties. Moreover, many TTMCs have lower structural symmetry and inversion symmetry breaking often occurs in their single layer forms, which, combined with strong SOC, can result in spin splitting. Therefore, 2D atomic crystals of TTMCs can reasonably be expected to exhibit distinctive properties. There are many layered, semiconducting layered TTMCs which allow combinations of 3d and 4d/5d/Sb/Bi, such as Cu₂MX₄ (M=W/Mo; X=S/Se) [4-7], Mn(Sb/Bi)₂S₄ [8-10] and (Mn/Fe)Bi₄S₇ [11]. Many of these materials have optical bandgaps in the visible range and their layered structures may allow accessibility of 2D atomic crystals. One major objective of this research project is to discover novel 2D TTMC materials with distinct and useful properties as well as establish the synthesis science of for the proposed TTMCs. The research work of this project includes bulk single crystal growth and characterization of TTMCs, preparation of 2D atomic crystals of TTMCs, nanoscale transport measurements, and the search for exotic properties on 2D TTMCs using field effect in transistors device. The PIs have performed preliminary studies on some layered TTMCs such as Nb₃SiTe₆ and Ta₂Pd₃Se₈; few-layer 2D crystals were found to be accessible and stable for both systems. In addition, the PIs also plan to search for high temperature superconductivity on 2D nanocrystals of iron chalcogenides $Fe_{1+v}(Te_{1-x}Se_x)$ using field effect in double gated transistor devices.

Recent Progress

Under the motivation that ternary 2D materials may exhibit exciting properties as discussed above, the PI have attempted synthesizing several layered, ternary materials, including MnPS₃, FeNbTe₂, Nb₃SiTe₆, Ta₂Pd₃Se₈ and Ta₂NiSe₅ using flux and chemical vapor transport methods. These efforts have been very successful; high-quality single crystals have been obtained for all of them. Figure 1a-e shows their crystal images. Crystals of MnPS₃, FeNbTe₂,

 Nb_3SiTe_6 and Ta_2NiSe_5 show lamellar shapes, consistent with their layered structures. Crystals of $Ta_2Pd_3Se_8$ are needle-like, consistent with its quasi-one-dimensional structure.



Figure 1: Crystal structures (top panel), optical crystal images (middle panel) and AFM image (bottom) of layered ternary transition metal chalcogenides MnPS₃ (a), FeNbTe₂ (b), Nb₃SiTe₆ (c), Ta₂NiSe₅ (d), and Ta₂Pd₃Se₈ (e).

The PIs have explored the accessibility of 2D thin layers of these materials and demonstrated 2D atomic thin layers are indeed accessible for MnPS₃, FeNbTe₂, Nb₃SiTe₆ and Ta₂NiSe₅ via microexfoliation. The bottom panels of Fig. 1 show micrographs of tri/bi-layer thin flakes of these materials. Given these materials show diverse bulk properties, their atomically thin layers offer fertile ground for exploring novel functional properties of 2D materials.

 $MnPS_3$ is an antiferromagnetic (AFM) insulator with the Neel temperature of 78 K [12]. Theoretical studies have suggested that the entagle of antiferromagnetism and valley degree of freedom in the monolayer $MnPS_3$ may lead to lifted spin degeneracy [13]. 2D atomic crystals of MPX_3 are accessible, as shown in Fig. 1a. We also demonstrated bulk $MnPS_3$ single crystals display photoluminienscene.

FeNbTe₂ and Ta₂NiSe₅ are also layered materials with Van der Waals (vdW) gaps (see Fig. 1b and 1c). FeNbTe₂ is a small gap semiconductor ($\Delta \sim 0.5$ eV) with an AFM order involving competing AFM and FM interactions [14], whileTa₂NiSe₅ is a candidate for excitonic insulator [15] and shows metal-to-semiconducting transition near 500K [16]. Atomic crystals are accessible for both materials.

 $Ta_2Pd_3Se_8$ possesses a quasi-1D structure and its electronic properties of $Ta_2Pd_3Se_8$ have not been reported. The PIs have shown that the single crystals of this materials can be easily exfoliated to stable nano-wires with the smallest diameter reaching ~ 1.5 nm and such nano-wires exhibit semiconducting properties with the gap being ~ 1 eV. The accessibility of such stable 1D nano wires offers wonderful opportunities to explore transport properties in 1D limit. We have already observed impressive transistor performance in a nano-device based on a $Ta_2Pd_3Se_8$ nano wire (see Fig. 2).



Figure 2: (a) SEM image of $Ta_2Pd_3Se_8$ fiber bundles. Upper insert shows the crystal structure projected along c axis. (b) AFM image of a $Ta_2Pd_3Se_8$ nanowire device. The wire is exfoliated from a bulk crystal. The insert at the bottom left shows the height profile. (c) Transconductance of a $Ta_2Pd_3Se_8$ nanowire device measured at room temperature.

In our previous work, we also found Nb₃SiTe₆ atomic crystals show unusual quantum transport properties, which provides strong evidence for a long-standing theoretical prediction-electron-phonon interaction is suppressed by dimensionality confinement on phonons [17-18]. This work has recently published in *Nature Physics*[19].

Our accomplishments obtained in the preliminary studies demonstrate that layered ternary materials would offer rich opportunities for exploring novel functional properties in the 2D world.

Future Plans

The research work of this project includes bulk single crystal growth and characterization of TTMCs, preparation of 2D atomic crystals of TTMCs, nanoscale transport measurements; and the search for exotic properties on 2D TTMCs using field effect in transistor devices.

<u>Single crystal growth</u>: The Mao (PI) group has a strong background in single crystal growth of various materials using the floating-zone, flux and chemical vapor transport (CVT) techniques. We have successively synthesized single crystals for MnPS₃, FeNbTe₂, Nb₃SiTe₆, Ta₂Pd₃Se₈ and Ta₂NiSe₅. Future efforts towards crystal growth will be extended to other interesting materials, including Cu₂MX₄ (M=W/Mo; X=S/Se)[4-7], Mn(Sb/Bi)₂S₄[8-10] and (Mn/Fe)Bi₄S₇ [11], using various approaches mentioned above.

<u>Structure and bulk properties characterization</u>: We will use x-ray diffraction and an energy dispersive x-ray spectrometer to characterize the structures and compositions of the synthesized materials, respectively. Band gap and carrier mobility are two important parameters for semiconductor devices, since the former affects the on-off ratio and the off-state power consumption rate of a device, while the latter is crucial for high speed response. We will perform resistivity measurements on synthesized crystals and estimate their electronic band gap from the fits of temperature dependence of resistivity in high temperature ranges. Together with Hall effect measurements, we can also evaluate the mobility of these bulk samples. Additionally, we will also conduct specific heat and thermal conductivity measurements on synthesized single crystals to examine their thermodynamic properties.

For the proposed materials containing magnetic ions, such as $Mn(Sb/Bi)_2S_4$, $(Mn/Fe)Bi_4S_7$ and MPS_3 (M=Fe, Ni and Mn), we will also investigate their magnetic properties by magnetization and magneto-transport measurements.

<u>Nanoscale transport measurements</u>: Once these 2D TTMCs bulk single crystals with characterized properties become available, we will use microexfoliation [41, 141] to produce 2D atomic crystals for nanoscale transport measurements. We have made various technical improvements, such as the pretreatment of the substrate to enhance the surface adhesion for better exfoliation. Additionally, we have developed a new approach, i.e., using low energy ion milling to thin down crystals with atomic level precision.

The obtained 2D atomic crystals will be characterized by Atomic force microscopy (AFM), Raman spectrum, and transmission electron microscopy (TEM). In addition, we will also exam the stability of the obtained 2D atomic crystals using the above characterization techniques. Then we will study the electronic transport properties of atomically thin materials of TTMCs. Electronic transport measurements will be performed on multi-terminal electronic devices prepared on 2D TTMC crystals obtained by microexfoliation or ion milling combined with electron-beam or photo lithography.

We will fabricate the field effect transistor (FET) devices based on TTMCs semiconductors and study their potential electronic and optoelectronic applications (for example, we have recently demonstrated FET device based on new ternary material $Ta_2Pd_3Se_8$, see Fig. 2). We will also search for exotic emerging quantum properties of 2D TTMC and $Fe_{1.02}(Te_{1-x}Se_x)$ atomic crystals using field effect in double gated transistor devices.

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Publications

We just started this project from Sep, 2015 and have not had any publications yet.

Growth of InGaN Quantum Dots by Liquid Phase Epitaxy (LPE) in an MBE Reactor

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Program Scope

This research program is focused on the investigation of surface-plasmon-enhanced light emission and absorption in semiconductor photonic materials coupled to metallic nanostructures. The specific efforts described below are aimed at the development of a materials platform that can optimally enable these investigations, i.e., InGaN quantum dots (QDs) with composition across the entire alloy range. These materials are ideally suited to the study of plasmon-matter interactions, because of their widely tunable bandgap energies across the visible spectrum (where the plasmonic resonances of typical metallic nanostructures occur) and favorable near-surface radiative properties (unlike other III-V semiconductors which are limited by Fermi-level pinning). InGaN QDs are also technologically significant for a wide range of applications that could benefit strongly from these plasmonic interactions, including all-solid-state lighting and photovoltaics based on the intermediate-band device concept. In addition, the use of highly localized QDs in low-density samples would allow for the direct probing of the giant opticalfield enhancements produced by metallic nanoparticles in their near-field vicinity. Other recent activities in this program, focused on the directional control of light emission and photodetection with plasmonic metasurfaces, are summarized in a separate abstract.

Recent Progress

The traditional method of forming semiconductor QDs is the strain-driven Stranski-



Krastanov (SK) method [1]. The SK growth mode relies upon accumulated in-plane compressive strain in order to induce a transition from 2D to 3D growth. This method by nature has a number of limitations, since there is an optimum amount of strain required for the formation of QDs and therefore it is impossible to decouple wetting layer thickness, QD composition, QD dimensions, and template material from one another. This method has also been used extensively for the development of GaN QDs and InGaN QDs [2, 3]. However, because InGaN alloys tend to undergo phase separation by spinodal decomposition as shown in Figure 1(a) [4], the aforementioned limitations of the SK growth method do not allow for the fabrication of InGaN QDs in the entire alloy composition. For high In-content InGaN QDs on GaN the resulting SK QDs are fully incoherent or defective.

In this project we are developing a novel method of forming InGaN QDs. This method relies upon our ability to form

an In-Ga liquid solution in the entire compositional range at relatively low temperatures. As seen in the phase diagram of Figure 1(b), a mixture of In and Ga has a single liquid phase above temperatures ranging from a minimum of $15 \,\text{C}$ for 14% In (at the eutectic point) to a maximum of $157 \,\text{C}$ for 100% In [5].

Upon simultaneous or sequential deposition in an MBE chamber of In and Ga on a substrate, the In and Ga adatoms form a liquid solution, whose composition is controlled by the ratio of the fluxes of the two constituents ($F_{In}/F_{In}+F_{Ga}$). Thus, the control of the composition by this method avoids the complex relationship between strain and chemical potentials that governs the SK growth mode. The nucleation of this liquid film on the substrate is governed by the interfacial free energy between the liquid deposit and substrate σ_{ds} , the liquid deposit and vapor σ_{dv} , and the vapor and substrate σ_{vs} . At equilibrium the liquid deposit forms a hemispherical cap on the top of the substrate and the contact angle θ is given by the expression $\cos \theta = (\sigma_{vs} - \sigma_{sd}) / \sigma_{dv}$ [6].

If σ_{vs} - $\sigma_{sd} = \sigma_{dv}$ then θ =0 and the deposit is said to wet the substrate and form a continuous liquid film. So far we have investigated the deposition of In-Ga solution on GaN and AlN templates. In both cases we found that the In-Ga liquid solution forms nano-droplets on the top of the substrate.

After the formation of the In-Ga liquid nano-droplets, active nitrogen (N, N^+ , N_2^*),



produced in an RF plasma source, is used to convert the In-Ga nanodroplets into InGaN QDs. These QDs are expected to have the same composition as the In-Ga nano-droplets. It should be pointed out that although the solubility of molecular N2 in Ga at the growth temperature of InGaN alloys is very low, the solubility of active N is expected to be very high [7]. It should also be stressed that LPE, in general, is a thermodynamic process, and thus, one expects the produced InGaN QDs to be of higher crystalline quality, compared to the SK growth mode which is kinetically controlled.

Our LPE growth method has effectively produced InGaN QDs across a range of growth parameters. Figure 2 shows representative AFM and SEM images of LPE InGaN QDs on AlN. In-plane grazing incidence x-ray diffraction (IP-GID) showed the QDs to be coherent to the AlN template. Due to the thinness of the QD layers, conventional high resolution x-ray diffraction was found to be unsuitable for the compositional analysis. We have however observed a shift of the critical angle (α_c) in x-ray scattering

experiments that is consistent with the relative electron densities. We are currently investigating x-ray reflectivity for compositional analysis, as it can probe α_c with high resolution.

We have also developed the capability for in-house lab-scale grazing incidence small angle x-ray scattering (GISAXS) characterization of single- and multi-layer QD samples.

GISAXS traditionally relies upon access to synchrotron radiation at a beamline, which forces a significant delay between growing a sample and producing meaningful data. We have uniquely incorporated advanced GISAXS techniques into our standard characterization procedure for single- and multi-layer QD samples, enabling effective determination of parameters such as the dimensions, shape, lateral and vertical correlation, and areal density. The technique is non-destructive and integral, and as such perfectly complements the destructive and localized TEM technique that we also have access to.

The correlation length (L) and areal density (ρ_N) of several LPE grown samples were investigated as a function of flux ratio, approximate thicknesses D, and template material. All samples were grown with a substrate temperature of 300 °C during all stages of the growth. GISAXS was performed with incident angle $\alpha_i = .5$ degrees. This exceeds the critical angle of InN, GaN, and AlN, and thus yields quasi-kinematical scattering behavior [8]. Experiments were performed with the incident beam along the [10-10] and the [11-20] directions. The Table below shows the growth parameters and the values of L and ρ_N .

Sample	Substrate	$F_{In}\!/F_{In}\!+\!F_{Ga}$	Thickness D (nm)	Correlation length L (nm)	Areal density ρ_N (cm ⁻²)
V3581	GaN	.61	6.03	36.86	7.36×10^{10}
V3584	GaN	.62	2.03	33.20	9.07×10^{10}
V3604	AlN	.62	2.03	30.44	1.08×10^{11}
V3605	AlN	.62	1.35	31.51	1.07×10^{11}
V3610	AlN	.40	2.02	42.76	5.47×10^{10}
V3611	AlN	.40	1.35	51.63	3.75×10^{10}
V3613	AlN	.21	2.04	48.87	4.19×10^{10}

L and ρ_N were determined from the analysis of horizontal slices of the GISAXS patterns along the Yoneda wing as shown in Figure 3. Figure 3 (a) shows the GISAXS pattern of sample V3613 with annotated descriptions of the various features and the extracted intensity vs q_y plot is shown in Figure 3 (b). L was calculated from the q_y positions of the correlation peaks, using $L = 2\pi/q_y$. ρ_N was approximated using $\rho_N = (1/L)^2$. For all samples, L was found to be almost identical for both azimuthal orientations and the tabulated values are the averages of the two [9].



Future Plans

Future work will focus on the optoelectronic properties of the LPE InGaN QDs, including their use for intermediate-band photovoltaics. These samples will then be combined with the plasmonic nanostructures which are also under development in this program, for the further investigation of plasmon-enhanced light emission and absorption. The tunability of ρ_N will also be explored to make low areal density samples, for the study of highly localized plasmon-matter interactions.

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Publications

J. DiMaria, E. Dimakis, T. D. Moustakas, and R. Paiella, "Plasmonic off-axis unidirectional beaming of quantum-well luminescence," <u>Appl. Phys. Lett.</u> 103, 251108 (2013).

W. Pan, E. Dimakis, G. T. Wang, T. D. Moustakas, and D. C. Tsui, "Two-dimensional electron gas in monolayer InN quantum wells," <u>Appl. Phys. Lett.</u> 105, 213503 (2014).

R. Paiella, "Plasmonic control of quantum-well luminescence for enhanced efficiency and beam shaping," <u>35th Progress in Electromagnetics Research Symposium</u>, Guangzhou (China), 2014 (**Invited Talk**).

T. D. Moustakas, "Fundamental differences between cubic III-V compounds and wurtzite nitride semiconductors produced by molecular beam epitaxy," <u>18th International Conference on</u> <u>Molecular Beam Epitaxy</u>, Flagstaff (Arizona), September 2014 (**Plenary Talk**).

J. DiMaria, E. Dimakis, T. D. Moustakas, and R. Paiella, "Plasmonic collimation and beaming from LED active materials," <u>IEEE Conference on Lasers and Electro-Optics</u>, paper CF2E.2, San Jose (CA), 2013.

T. D. Moustakas, "Fundamental differences between traditional III-V compounds and Nitride Semiconductors" <u>11th Int. Conf. on Nitride Semiconductors</u>, Beijing, China, Sept., 2015 (**Invited Talk**)

Project Title: Thermochemistry of Oxides with Electrochemical and Energy Applications

Grant number: DEFG0203ER46053

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Program Scope

The focus of the current project is to emphasize the thermodynamic properties of materials relevant to energy conversion. The main objectives are: (a) to advance and use unique calorimetric capabilities to determine the energetics of oxide and other materials having possible energy applications, with an emphasis on new materials for batteries, fuel cells and solar energy conversion, (b) to understand, in terms of both macroscopic energetics and microscopic structure and bonding, the interplay of defect chemistry, oxidation-reduction, and size effects at the bulk and nanoscale in determining materials properties. This project emphasizes mixed ionic - electronic conducting materials containing transition metals (M) of variable valence, especially perovskites and lithium containing phases, with M = Mn, Fe, Co, Ni. The thermochemistry of new families of complex halide, chalcogenide, nitride, and hybrid (organic-inorganic) perovskite materials are being explored. The major and unique technique employed is high temperature oxide melt solution calorimetry, with careful attention given to materials synthesis and characterization.

The materials under study find important applications in solid oxide fuel cells, gas separation membranes, catalysts, batteries, and solar energy, as well as nuclear energy and aerospace technologies. Thus they are directly relevant to one of the Department of Energy's basic missions, namely the development of more efficient energy sources and energy utilization. Fundamental and systematic thermodynamic data are essential for predicting possible new materials, for determining materials compatibility and longevity as well as use-inspired fundamental questions. In addition, the project trains students and postdocs in careful measurements and rigorous data analysis and in working in a large multi-disciplinary group to prepare them for careers in the materials science of energy. This project is leveraged by a number of international collaborations, which both extend the science and provide opportunities for students and postdocs to work in a global environment.

Recent Progress

Although the current renewal started this July, we have already made progress in several areas and here we highlight work related to hybrid perovskites, which have gained considerable interest for their applications in photovoltaics and multiferroics.

<u>Dimethylammonium metal formates</u> [DMA-M-F]: We have synthesized, characterized, and measured the heats of formation of a series of isostructural dimethylammonium metal formate perovskites, $[(CH_3)_2NH_2][M(HCOO)_3]$ with M = Ni, Mn, Zn and Co, which have shown promising multiferroic behavior. Their enthalpy of formation from components becomes less exothermic in the order Mn, Zn, Co, Ni (Table 1). The stability of the hybrid perovskite decreases as the tolerance factor increases,

unlike trends seen in inorganic perovskites.

[DMA-M-F]	Enthalpy of	Tolerance	Cation radius ^a
	formation	factor	□(pm)
	(kJ/mol)		
[DMA-Mn-F]	- 47.95±1.12	0.941	83
[DMA-Co-F]	-34.89±0.68	0.968	74.5
[DMA-Ni-F]	-28.45±0.25	0.986	69
[DMA-Zn-F]	-41.66±0.66	0.970	74

Table 1. Calculated tolerance factors of [DMA-M-F] hybrid perovskites and their formation enthalpies



Our study shows that the stability of $[(CH_3)_2NH_2][M(HCOO)_3]$ hybrid perovskites, is comparable to those of a number of inorganic ternary oxides (Fig 1). Among the four isostructural compounds we studied, the Mn analogue is most stable, followed by Zn, Co, and Ni. The energetics of these ternary transition metal materials seem to be governed more by the acid–base properties of the associated moiety and the transition metal oxide than by a bond length misfit as measured by the tolerance factor. <u>Metal formates</u>: The simplest organic - inorganic hybrid materials are metal formate, with divalent cations connected by formate anions. They show great potential for applications in gas storage and Li-ion battery materials. We report synthesis, characterization, and enthalpies of formation of five isostructural metal formates, $M(HCOO)_2 \cdot xH_2O$ with M = Mg, Mn, Co, Ni and Zn. The enthalpies of formation of $Mg(HCOO)_2 \cdot 2.12H_2O$, $Mn(HCOO)_2 \cdot 2.02H_2O$, $Co(HCOO)_2 \cdot 1.85H_2O$, $Ni(HCOO)_2 \cdot 2.13H_2O$ and $Zn(HCOO)_2 \cdot 2.08H_2O$ are -91.27 ± 1.86 , -64.26 ± 1.04 , -49.68 ± 0.90 , -38.30 ± 0.92 , -70.01 ± 0.88 kJ/mol, respectively. The stability of the metal formates follows the order: Mg > Zn > Mn > Co > Ni.

<u>Methylamine lead halide perovskites</u>: CH₃NH₃PbX₃ is a light-harvesting material proposed for organic-inorganic hybrid perovskite solar cells (PSC). Sensitivity towards moisture of these materials is a potential drawback in practical applications. We are currently working on the synthesis, characterization and calorimetry of methylamine lead halide perovskites, MAPbX₃ [X = I, Br]. Thermodynamic data will help establish the best compositions and conditions for synthesis, stability and applications.

Inorganic rare earth perovskites: We have completed work with our Romanian colleagues on rare earth cobaltite and ferrite - manganite perovskites applicable to solid oxide fuel cells and this work is now published or in press. Lanthanide cobalt perovskites $LnCoO_{3-\delta}$ (Ln = La, Nd, Sm, and Gd) are important materials for electroceramics, catalysts, and electrodes in solid oxide fuel cells. Formation enthalpies of $LnCoO_{3-\delta}$ compounds were measured using high temperature oxide melt solution calorimetry. The formation enthalpies of $LaCoO_{2.982}$ and $GdCoO_{2.968}$ from constituent binary oxides (Ln_2O_3 , CoO) and O_2 gas are 111.87 1.36, 98.49 1.33, 91.56 1.46 and 88.16 1.45 kJ/mol , respectively. Thus these perovskites become energetically less stable with decrease in ionic radius of the lanthanide (from La to Gd), which corresponds to a decreasing tolerance factor and increasing oxygen deficiency. The thermodynamic stability of $LaCoO_{2.992}$, $NdCoO_{2.985}$, $SmCoO_{2.982}$ and $GdCoO_{2.992}$, $NdCoO_{2.985}$, $SmCoO_{2.982}$ and $GdCoO_{2.968}$ correlates well with that expected from their tolerance factors and oxygen partial pressures corresponding to their decomposition.

Future Plans

Antiperovskites: These are ternary halides with cubic structure with the general formula AXM₃, where A is oxygen, X is halogen and M is Li –These are being considered as solid electrolytes in Li Ion batteries. The metastability of Li₃OX relative to Li₂O based on DFT calculation indicates that they are subject to decomposition under applied voltage. Hence directly measured formation enthalpies will help in understanding the phase stability of these electrolytes.

Tin halide perovskites: Tin halide perovskites have attracted attention a promising class of materials for optoelectronic applications. Their systematic thermochemistry is not known and we plan to study their heats of formation.

Rare earth hybrid perovskites: The rare earth elements are important components in materials used in sustainable energy and high technology applications. Several rare earth metal compounds containing formate with the composition $(FA)_2Ln(HCOO)_3 \cdot xH_2O$ (where $x = \theta \cdot 2$, FA = HCONH₂ and Ln = La-Lu, Y) are considered as materials relevant for rare earth recovery from end-of-life products and also are important as phosphors. Understanding their thermodynamic properties is hence important and we will start a study of their heats of formation.

Mixed anion lithium ion battery materials: We are continuing thermochemical studies of transition metal compounds containing Li and sulfate, halide, and hydroxide groups prepared by J.-M. Tarascon in France

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Program Title: Exploring superconductivity at the edge of magnetic or structural instabilities

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Project Scope:

Modern research of condensed matters devotes in understanding how properties of complex solids are determined by their structural and electronic degrees of freedom. Despite of the complicity in real materials where competing orders often exist, significant progress has been driven by the discovery of new materials with emergent ground states. The recent discovered Febased superconductors (FBS), together with the cuprates, are the only two high Tc superconducting families in the world. Although they differ in various ways, both of them are quasi two dimensional materials at the edge of structural/magnetic instabilities. The discovery and characterization of materials of this type can advance our understanding of high Tc superconductivity significantly. The objective of this research is to discover superconductors that lie at the edge of structural/magnetic instability using solid state reaction and crystal-growth methods, and to characterize them and examine their structure-property relations through thermodynamic, transport, X-ray, and neutron measurements.

Recent Progress:

1. We have successfully grown and characterized two new series of Fe-based superconductors, the Co and Ni doped 10-3-8 superconducting family using the high

temperature flux-growth method. The structural/magnetic phase transitions in the parent compound were suppressed to lower temperature and superconductivity up to 15 K occurs. Single crystal quality has been significantly increased, indicating by a clear specific jump at Tc. The comparison between the two families shows rigid band approximation is applicable here. Tc is relatively lower in Ni doped 10-3-8, may be due to the strong impurity scattering from Ni atoms comparing to Co dopants.



2. We have attempted to grow the BaTi₂Bi₂O single crystals, which has CDW around 200 K and became SC at ~10 K when Na is doped. Although we failed in this trial, we discovered a new suboxide, $Ba_{1+\delta}Ti_{13-\delta}O_{12}$ ($\delta = 0.11$) [2]. It is a paramagnetic poor metal with hole carriers dominating the transport. Fermi liquid behavior appears at low temperature. The oxidization state of Ti obtained by the XAS is consistent with the

metallic Ti²⁺ state. Local density approximation band structure calculations reveal the material is near the Van Hove singularity.

The pseudogap behavior in the Ti-d band and the strong hybridization between the Ti-d and O-p orbitals reflect the characteristics of the building blocks of the



Ti₁₃ semi-cluster and the TiO₄ quasi-squares, respectively.

3. We have successfully grown and characterized high quality single crystals of Ca_{0.73}La_{0.27}FeAs₂, the "parent" compound of the 112 superconducting family for the first time using the high temperature flux growth method.

The Ca_{1-x}La_xFeAs₂ (CaLa112) Fe pnictide superconductors (FPS) shows the record bulk T_c up to 42 K in nonoxide FPS [1]. The breaking of C_4 rotational symmetry even at room temperature makes it unique among all FPS. The comparison of this CaLa112 with the other FPS will enable us to distill the important information on inducing high T_c . However, until now, no systematic study has been made on this system. Our comprehensive study of Ca_{0.73}La_{0.27}FeAs₂ single crystal established it is the parent compound of the CaLa112 FPS with structural/magnetic phase transitions. We unraveled the nature of both phase transitions and found a new stripe type magnetic structure. What's more, by studying Ca_{0.73}La_{0.27}FeAs₂, we established that this CaLa112 family is

characterized by the presence of metallic spacer layers and it is intrinsically structurally untwinned. Electronic nematicity has been argued to exist in both cuprate and FPS, which lowers the rotational symmetry but keeps the translational symmetry. It has been argued to be the origin of the



pseudogap in cuprate. In order to study the nematicity in FPS, uniaxial pressure/strain is usually used to detwin the sample. However, the external pressure itself already breaks the rotational symmetry, which has caused lots of debates on the origin of the observed in-plane anisotropy. The naturally detwinned 112 FPS provide a new avenue to examine the electronic nematicity in FBS. In addition, as the first tunable FBS with metallic layers, this material can also serve as a great platform to study the effect of metallic spacer layers on superconductivity.

The comparison of this material with the prototype 122 FPS is fruitful and revolutionary. The consensus of the Fe based superconductor is that the parent compound of the FPS is a semimetal with equal hole and electron carriers. The fact that the "parent" compound of CaLa112 is the apparently electron overdoped $Ca_{0.73}La_{0.27}FeAs_2$ is intriguing. A closer look into the ARPES data suggests a reasonable Fermi surface nesting exists in this electron-over doped material while the DMFT calculations indicate the Fermi surface nesting is enhanced when it is hole doped. This sheds light on the important role of both Fermi surface nesting and the superexchange interaction in the magnetism in FPS.

- **4.** We have made high quality Cd₃As₂ single crystals using the high temperature solution growth method for high pressure measurements [3]. Our collaboration with the high pressure group find that Cd₃As₂ undergoes a structural phase transition from a metallic tetragonal phase in space group I41/acd to a semiconducting monoclinic phase in space group P21/c at critical pressure 2.57 GPa, together with this structural phase transition, a metallic to semiconducting behavior is observed, indicating a breakdown of this 3D Dirac semimetal.
- 5. We have grown high quality (Ca_{1-x}La_x)₁₀(Pt₃As₈)(Fe₂As₂)₅ single crystals using the high temperature solution growth method to study the doping-dependent superconducting gap structure by measuring the in-plane London penetration depth [4]. The gap is isotropic close to the optimal doping,—a trend commonly found in charge-doped FeSCs. While there is no evidence for the static microscopic coexistence of superconductivity and magnetism in the underdoped regime in this compound, the gap anisotropy increases dramatically in the underdoped regime which may suggest a possibility of either dynamic or much finer scale coexisting superconductivity and short-range magnetic correlations.

Future Plans:

- 1. The double doping study of $Ba(Fe_{1-x}Co_x)_2(As_{1-y}P_y)_2$. We will use Ba_2As_3 flux to grow single crystals of this kind to explore the quantum criticality of in this system. Transport and thermodynamic measurements will be performed.
- 2. The recent discovery of increased T_c in KFe₂As₂ under high pressure up to 20 Gpa has been argued to be due to the enhanced superconducting pairing in collapsed tetragonal FeAs phase. On the other hand, the collapsed tetragonal phase has been believed and proved to be harmful for spin fluctuation and thus superconductivity in CaFe₂As₂. Therefore, it is important to clarify the relation between superconductivity in collapsed tetragonal phase. The Na_{1-x}La_xFe₂As₂ system has the potential to be a chemical-doping analog of the pressure-induced KFe₂As₂. We will grew single crystals and do systematic study of this series.
- 3. It has been a long-time debate if the magnetism in FBS is localized or itinerant. Recent study on the Na(Fe_{1-x}Cu_x)As shows a Mott insulator phase at x=0.5 doping, providing strong evidence that FBS is near to Mott phase. We would like to investigate if this is in general for all FBS or just specific for NaFeAs system. We plan to study Cu doped 1038 to and use elastic neutrons scattering to study the possible magnetism inside.

4. The interplay between SC and magnetism in collapsed tetragonal phase in double doped CaFe₂As₂. CaFe₂As₂ is special in 122 because of the existence of collapsed tetragonal phase in it when chemical doping/pressure is applied, which is believed to be unfavorable for spin fluctuation and thus superconductivity. On the other hand, rare earth doped Ca122 shows trace superconductivity up to 45 K. We plan to use double doping trials to avoid the collapsed tetragonal phase and induced bulk superconductivity up to a record temperature.

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A Fundamental Study of Inorganic Clathrates and other Open-Framework Materials

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Program Scope

Inorganic clathrates exhibits a wide range of physical properties that can be tuned, or completely altered, with chemical composition. Relatively few compositions have however been investigated due to the formidable synthetic challenges in synthesizing most compositions. We have developed different synthetic techniques to overcome the serendipitous advances that traditional synthetic approaches allow and obtain targeted thermodynamically metastable compositions. Among the new synthetic approaches developed under this program spark plasma sintering (SPS) is unique in that a pulsed DC current is applied to the material directly while under uniaxial pressure. Our laboratory is one of only a few world-wide that is synthesizing materials, in microcrystalline as well as single-crystal form, by SPS. Together with our recently developed kinetically controlled thermal decomposition (KCTD) technique, we are able to synthesize new clathrate compositions, many for the first time. These techniques can also be employed for the synthesis and crystal growth of other intermetallic or metastable ternary and quaternary compounds.

Recent Progress

Our novel synthetic techniques have been employed in processing new multinary clathrate compositions that have until now not been obtained, and allowed for the investigation of their physical properties. Examples of recent progress include:



(i) Expanded the SPS and KCTD synthetic techniques to ternary and quaternary clathrate compounds as well as other open-framework materials.

(ii) The development of a new processing approach whereby ternary clathrate-II $A_8Na_{16}Si_{136}$ (A = K, Rb, Cs) single crystals were obtained by SPS via ion-exchange and electrochemical redox reactions between NaSi and ACl.

(iii) Expanding on (ii) in selectively synthesizing clathrate-I and -II compositions by changing the SPS reaction conditions. In addition, the synthesis of clathrate-I $K_{4,2}Na_{3,8}Si_{46}$ was achieved for the first time, and in single-crystal form, by this new multi-precursor approach.

Future Plans

We will expand on our KCTD and SPS techniques while continuing our investigation of new clathrate compounds. The new approach whereby more than one precursor is used, along with ion-exchange reactions during processing, will allow for the processing of new compositions. In

addition, Sn clathrate-II compositions that are of interest for thermoelectrics applications will be synthesized and their structural and transport properties investigated.

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FUNDAMENTALS OF SPARK-PLASMA SINTERING: MATERIALS PROCESSING FOR ENERGY APPLICATIONS

PI: Eugene A. Olevsky, San Diego State University, Award No. DE-SC0008581

Program Scope

The fundamental aspects of this research program are focused on the development of the theory of spark-plasma sintering (SPS) of powder components. SPS is a rapidly emerging powder consolidation technique capable of producing highly dense materials with a significant potential for grain size retention. SPS is based on the conjoint application of fast heating rates, high axial pressure and field (electric current - based) assisted sintering. Potentially, SPS has many significant advantages over the conventional powder processing methods, including the lower process temperature, the shorter holding time, dramatically improved properties of sintered products, low manufacturing costs, and environmental friendliness. Practical implementations of the SPS' bright potential, however, are limited by the lack of theoretical concepts enabling the process predictiveness and optimization.

This project's fundamental research activities are aimed at the determination of the SPS

dominant driving forces, contributing to the formulation of the general theory of spark-plasma sintering. Thereby the project specifically addresses the following issues: (i) modeling of the heat transfer during SPS of powder materials; influence of the heating rate on the consolidation and grain structure evolution; analysis of the impact of the thermal runaway effect on the "flash" sintering phenomenon; (ii) experimental de-convolution of the thermal and non-thermal phenomena occurring during SPS; (iii) coupled densification – grain growth –



processing (right) [1].

electromagnetic field – temperature distribution modeling at micro- and macroscopic levels; (iv) optimized (based on the developed model and experimental concepts) low-pressure SPS and free pressureless SPS processing and characterization of novel functionally structured porous nuclear fuel materials enabling the damage-free fission product escape.

The collaborative component of the proposed program involves interactions between SDSU and General Atomics - one of the world's leading resources for the high-technology systems development. The developed concepts are implemented in a novel modeling framework describing spark-plasma sintering for the optimization of the fabrication of functional porous structures of nuclear fuel for modular multiplier reactors. The porous structure is an essential element of the design of novel nuclear fuel pellets enabling fission product evolution. Thereby, the main applied aspects of the project are concerned with exploring the previously noninvestigated applications of spark-plasma sintering to the fabrication of structurally strong porous materials, which are of great interest for nuclear fuel and other energy-related applications [2-4].

Recent Progress

The PI's recently conducted research indicates that the understanding of the material

constitutive behavior during SPS is impossible without the analyses of mechanical consolidation, heat transfer and electric field-induced phenomena at multiple scale levels. The project introduces important mechanisms of both thermal and non-thermal nature in a novel generic micro-macro modeling framework for the description of sparkplasma sintering. The modeling activities are supported by unique experiments on the de-convolution of the heating rate -



driven and electromagnetic field - imposed effects at various scale levels. The developed new constitutive models of SPS and the interconnected codes at different analysis scales should ultimately lead to the creation of the generic multi-scale framework for modeling of spark-plasma sintering.

Based on the developed modeling framework, a novel tooling design, consisting in the



tailored drilling of axial cylindrical or ring-shaped holes within the punch, has been recently individuated and optimized through a campaign of fully coupled thermal, electrical and mechanical finite element simulations. The analysis of the numerical results, experimentally assessed, allows for a comprehensive understanding of the phenomena underlying radial temperature distributions in SPS and leads to the individuation of a technological solution for the uniformization of temperature distribution.

In addition, during the progress of the conducted project, new, exciting capabilities of SPS have been revealed, including the new potentially transformative Flash Hot Pressing (Flash SPS) approach, as well as the possibility of the SPS usage for seamless joining of ceramic and metallic materials.

Recent investigations conducted at SDSU showed that the consolidation efficiency can be

dramatically further improved by enabling an ultra-rapid "flash" regime of processing, when super-hard powder materials can be consolidated in a matter of few seconds. The idea of the "flash SPS" is based upon the idea of recently explored "flash sintering, however, it does not require the usage of higher voltage ranges, employed by "flash sintering" setups (and, therefore, not achievable in the industrially produced SPS devices.) Hence, flash SPS can be conducted in regular SPS



SEM micrograph of SiC powder (left), and SiC specimen processed by flash SPS (right)

devices. Flash SPS utilizes the theoretical idea of the thermal-runaway-based origin of the flash sintering phenomenon. As opposed to flash sintering, which should generally render uncontrollable clustered area heating of the processed specimen and therefore lead to highly spatially non-uniform distribution of temperature, density and of microstructure parameters, Flash SPS explores the possibility of the pressure-controlled thermal runaway, under which the mass transport driven by externally applied pressure should equalize the distribution of temperature and stabilize the process of consolidation. In contrast to flash sintering, which should have drastic scalability problems, Flash SPS has a potential of being employed for large scale specimens, where the uniformity of relative density and grain size is of great importance.

At SDSU, we have recently demonstrated the potential of SPS to produce practically seamless joints between SiC components without using any filler material. Both the localized and rapid heating contributed to the inherent energy saving of electric current assisted joining technique. Our preliminary results already showed that especially by rightly adjusting electric current, applied pressure and heating time, almost perfect joint within seconds can be obtained so that the heat-affected zone can be markedly reduced.



Joint with a visible seam (left) vs. seamless joint (right) between two SiC disks

Future Plans

The outcomes of the carried out work indicate the global nature of the targeted scientific problems. The achievement of the ultimate goal of the formulation of the general theory of spark plasma sintering requires the continuation of the initiated research in a systematic way identifying the contributions of all the thermal and non-thermal factors in the enhancement of mass transport under SPS processing conditions. Indeed, at the previous project stage, the emphasis has been made on the thermal factors acting during spark-plasma sintering and their de-convolution from the field-assisted phenomena. The impact of the electric current on the specifics of SPS, while being clearly confirmed by the fundamental comparative ("current-assisted" vs. "current-insolated") experiments, has not been incorporated in the constitutive

model of SPS. The SPS-specific non-thermal factors are related to the direct impact of electromagnetic field on the diffusion mass transport through electromigration, electroplasticity mechanisms, and dielectric breakdown of oxide films at grain boundaries.

These new developments and the need for a physically consistent modeling framework lend impetus to the continuation of the research on the fundamentals of spark-plasma sintering.

During the next stage of the project, the modeling and fundamental experimental efforts will be essential at multiple scale levels including the detailed meso-scale description of the electric current-affected pore-grain structure evolution coupled with a macro-scale reliable assessment of the processing of real-world macroscopic components. The main fundamental issues that will be addressed in the proposed program are: what is the contribution of the "non-thermal field effect" involved during SPS? How is the microstructure developed during current-affected processing? What is the physical basis of the ultra-rapid consolidation/joining? The developed constitutive concepts will be implemented in a novel multi-scale modeling framework describing spark-plasma sintering. The main applied aspects of the renewal proposal will be concerned with exploring the novel technologies of Flash SPS and SPS joining.

Thus, the planned future activities include the analysis of the SPS physical basis at multiple scales specifically exploring the role of electric current in the acceleration of mass transport and with an emphasis on ultra-rapid materials consolidation and joining.

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Publications

Refereed Journal Papers

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Plasmonic Metasurfaces for the Directional Control of Light Emission and Photodetection

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Program Scope

This program is focused on the development of novel plasmonic nanostructures designed to engineer the radiation and absorption properties of semiconductor photonic materials. Our key building blocks are metallic nanoparticles (NPs) fabricated by top-down lithographic techniques, acting as geometrically tunable optical antennas. These NPs can dramatically increase the spontaneous emission rate of an underlying active material, through the near-field excitation and subsequent radiative decay of their plasmonic resonances (i.e., collective oscillations of the NP electron gas). Under these conditions, the far-field radiation pattern of the emitted light can be tailored with remarkable flexibility by controlling the NP size, shape, and spatial distribution. By reciprocity, if the same nanostructures are fabricated on an absorbing material, they can be used to enhance the absorption strength and control it as a function of direction and polarization of the incident light. The study of these phenomena can shed new light on the unique optical properties of metallic nanostructures, while at the same time open the way to new device concepts and applications in optoelectronics.

Additional activities in this program are aimed at the development of a semiconductor materials platform that can optimally enable the investigation of such plasmonic interactions, i.e., InGaN quantum dots with composition across the entire alloy range. These materials are ideally suited to the proposed studies, because of their widely tunable bandgap energies across the visible spectrum (where the plasmonic resonances of typical metallic nanostructures occur) and favorable near-surface radiative properties. Furthermore, they are technologically significant for a wide range of applications, including solid-state lighting and photovoltaics, which could benefit strongly from the same plasmonic interactions. Our recent progress in this materials development effort is summarized in a separate abstract.

Recent Progress

Recent activities have focused on the design of complex NP arrays for the directional control of light emission and photodetection. Our main achievements, summarized in the following, include (1) the theoretical investigation of radiation processes in the near-field vicinity of gradient metasurfaces, and (2) the initial experimental demonstration of plasmon-assisted directional photodetection.

(1) LIGHT EMISSION NEAR A GRADIENT METASURFACE

Gradient metasurfaces (GMSs) have recently emerged from extensive research in nanophotonics as a powerful tool for the control of externally incident optical waveforms [1]. Their basic

geometry consists of a planar array of optical nanoantennas with sub-wavelength separation and spatially varying size, shape, and/or orientation, designed to introduce a linearly graded phase shift in the light reflected from and/or transmitted through the array. In recent years, GMSs have been used to demonstrate several remarkable functionalities, including anomalous reflection and refraction, light focusing in ultrathin lenses, and the generation of optical vortices [1].

In all of these prior efforts, the surface was illuminated with externally incident light having fixed wavevector and polarization. However, the unique properties of GMSs also appear to be ideally suited to the near-field control of radiation processes. In our recent work, this idea has been explored theoretically and then substantiated with rigorous full-wave simulations [2]. To describe the most general possible situation, we consider the homogenized continuum model shown in Fig. 1(a), which can be applied to any (reflective) GMS, regardless of the detailed implementation of the nanoantenna array. The light source is provided by a simple electric dipole, as appropriate to the description of spontaneous emission in typical luminescent media.



Fig. 1. (a) Schematic cross-sectional view of the system under study. The GMS is modeled with a perfect electric conductor (PEC) coated with an ultrathin metamaterial slab having position dependent permittivity ε and permeability μ , designed to produce a linear gradient $\xi \hat{\mathbf{x}}$ in the reflection phase shift. (b) Purcell enhancement factor of a dipole oriented along the *x*, *y*, and *z* directions [as defined in (a)] versus dipole lateral position along *x*. The Purcell factor is defined as $F_P = \Gamma_{\rm sp}/\Gamma_{\rm sp}^0$, where $\Gamma_{\rm sp}$ and $\Gamma_{\rm sp}^0$ are the dipole spontaneous emission rates near the GMS and in free space, respectively. (c)-(f) Far-field radiation patterns (i.e., optical intensity *I* versus emission angles) produced by a *z*-oriented dipole for $\xi/k_0 = 0.2$ (c), 0.6 (d), 1.0 (e), and 1.4 (f). Here k_0 is the free-space wavenumber. In each plot, the radial distance from the origin corresponds to the polar angle, while the direction on the circle corresponds to the azimuthal angle. Each color map is normalized to its peak value.

Our results show that the dipole radiation output is dramatically affected by the nearby GMS, in several important and unusual ways. First, the spontaneous emission decay can be strongly accelerated, by an amount that depends on the dipole lateral position in an oscillatory fashion [Fig. 1(b)]. Second, highly asymmetric directional radiation patterns can be produced with broad geometrical tunability of the angle of peak emission [Figs. 1(c)-1(f)]. Furthermore, the total output radiation power can be increased in the case of low-efficiency emitters, or quenched in favor of asymmetric surface-wave excitation depending on the GMS phase gradient.

Importantly, these phenomena could not be explained simply in terms of anomalous reflection of externally incident dipole radiation by the GMS. Instead, they highlight a unique near-field behavior of GMSs, related to a strong coupling between evanescent and propagating waves enabled by the GMS phase gradient. In addition, these results suggest a novel approach to control the output of radiation processes directly at the source level, without the need for any external optics. This ability has significant technological potential for future applications involving, e.g., nanoscale and high-speed light emitting devices, photonic integrated circuits, and highly multiplexed fluorescence sensors.

(2) PLASMON-ASSISTED DIRECTIONAL PHOTODETECTION

During prior work in this project, we have demonstrated the use of plasmonic NP arrays to produce geometrically tunable unidirectional light emission [3]. As shown in Figs. 2(a) and 2(b), the basic device geometry developed in this work consists of a semiconductor active layer coated with an ultrathin metal film supporting a periodic array of metallic NPs. In this geometry, light emission occurs via a two-step process, where surface plasmon polaritons are first excited on the metal film by the active layer and then scattered into radiation by the NPs. The far-field pattern of the emitted light can then be engineered by controlling the NP size, shape, and periodicity. With this approach, we have demonstrated the generation of highly collimated optical beams, emerging from the sample surface along a single direction determined by the array design.



Fig. 1. Plasmonic nanostructures designed to produce unidirectional light emission/absorption (a) along the sample surface normal, and (b) along a single geometrically tunable oblique direction. (c) Red trace: photocurrent I_p of a device based on the design of (a) versus angle of incidence θ of the detected light. Blue trace: photocurrent pattern of a similar device without any NP array. Both photocurrent patterns have been normalized to unit peak value.

By reciprocity, if similar nanostructures are fabricated on an absorbing layer, only light incident along a single geometrically tunable direction would be absorbed. In order to investigate this novel phenomenon, recently we have developed suitable samples where the NP arrays are fabricated between the electrodes of standard photoconductive devices. The red trace in the polar plot of Fig. 2(c) is the photocurrent of such a sample based on the design of Fig. 2(a), measured as a function of the angle of incidence of the incoming light. Highly directional photodetection along the sample surface normal is clearly observed. By comparison, a much broader pattern is obtained if no NP arrays are employed, as shown by the blue trace in Fig. 2(c).

We are currently in the process of fabricating similar samples based on the triangular NPs

of Fig. 2(b), to demonstrate directional photodetection along arbitrary off-axis angles. It should be noted that these devices are functionally analogous to the individual elements (ommatidia) of compound eyes, which represent the most prevalent vision modality in nature. Therefore, this research may lead to development of image sensors with the unique attributes of compound-eye vision (including large fields of view, nearly infinite depth of focus, and high acuity to motion), but in a flat ultrathin package. The same nanostructures may also find important applications in the areas of solid-state smart lighting and photovoltaics.

Future Plans

Both research thrusts above will be continued going forward. Specifically, we are now setting up an experimental effort to investigate the unique properties of GMSs for the control of light emission in their near-field zone, as predicted by our recent simulations. Furthermore, we will continue our current work towards the full demonstration of the "plasmonic ommatidia" just described. Finally, these and similar nanostructures designed for the plasmonic control of radiation and absorption processes will be integrated with the InGaN quantum-dot samples that are also under development within this program.

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New Oxide Materials for an Ultra High Temperature Environment (DE-SC0010477)

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Program Scope

The development of ceramics that provide a robust performance in an aggressive high temperature environment is a continuing challenge. Materials for high temperature environments must satisfy several stringent requirements that dictate a high melting temperature and stability in an oxidizing environment that often contains water vapor as well as other compatibility issues. The available ceramics such as zironates, sialons, diborides or carbides satisfy some of the requirements such as high melting temperature, but they also exhibit limitations such as a high oxidation rate or surface decomposition especially in the presence of water vapor

What is needed for enhanced high temperature capability are new oxide materials. From the existing experience we are pursuing a new strategy that involves internal modification control of the outer surface to promote enhanced oxidation resistance. The internal modification focuses upon the development of a new oxide type based upon $Hf_6Ta_2O_{17}$ (HfTaO superstructure) and $Zr_6Ta_2O_{17}$ superstructures which lowers the oxidation rate. The oxide superstructures are metastable in the binary Hf-O and Zr-O systems, but experiments confirm that they can be stabilized by Ta additions.

The research focus is on a systematic fundamental study of the phase stability, defect structure and reaction kinetics of the oxide superstructures. The program also includes an investigation of the oxide superstructures constitution, the development of a microstructure based kinetics model for the oxidation behavior of multicomponent composites and an evaluation of the thermal barrier characteristics.

Recent Progress

1. Oxidation synthesis of HfTaO superstructure from Hf-Ta alloy.

The HfTaO superstructures can be synthesized via direct oxidation of Hf-Ta binary alloys with certain compositions (Fig. 1). The XRD investigation of the oxidation products shows that the direct oxidation of Hf-26.7Ta (atomic percent) and Hf-34.7Ta alloys can lead to the synthesis of HfTaO superstructures, while for Hf-Ta alloys with other compositions, the oxidation products are either HfO₂ excess (Hf-19.7Ta) or Ta₂O₅ excess (Hf-49.6Ta). The examination of the cross section microstructures of oxidized Hf-Ta alloys unveils a novel multistep oxidation process (Fig. 2), in which, a three layered microstructure is developed with the single phase oxide, a reaction layer composed of Hf-rich oxide phase and Ta-rich phase and a two phase of Hf-rich phase and Ta-rich phase region forming by a displacement reaction layer indicates that the substrate Hf-rich phase is preferentially oxidized while the Ta-rich phase is almost

unaffected. The interface between the reaction layer and the oxide indicates that the Ta-rich phase is gradually oxidized and forms a solid solution with Hf-rich oxide and finally yields the single phase oxide superstructure.



To elucidate the structural evolution during the oxidation synthesis of the HfTaO superstructures, a depth profile for the oxidized Hf-26.7Ta sample was constructed by carefully polishing the sample from the oxide surface to the substrate. At selected depths, XRD analysis was applied to identify the crystal structure of each phase (Fig. 3). It is evident that along the oxygen diffusion direction, the outer oxide layer is the HfTaO superstructure, the reaction layer is monoclinic HfO₂ and body-centered cubic (BCC) Hf-Ta solid solution, and the substrate is close-packed hexagonal (HCP) Hf-O solid solution and BCC Hf-Ta solid solution. Thus, the oxidation process is summarized as: Hf-Ta (solid solution, ss) \rightarrow HCP Hf-O (ss) + BCC Hf-Ta \rightarrow monoclinic HfO₂ + BCC Hf-Ta \rightarrow HfTaO superstructure (orthorhombic).



Moreover, this multistep oxidation process is not only observed in the Hf-26.7Ta alloy but also it is widely observed for other compositions in a wide temperature range (1200°C to 1650°C). It is also observed in the Zr-Nb system and leads to the formation of a ZrNbO supserstructure.

2. Thermodynamic evaluation of Hf-Ta-O ternary system.

Based on the oxidation process of Hf-Ta alloy, a thermodynamic evaluation of Hf-Ta-O system was conducted (Fig. 4). The evaluation is based upon the reported thermodynamic data[1,2] and treats the superstructure as a line compound. The initial calculated isothermal section at 1500°C corresponds well with the experimentally observed reaction path (Fig. 4), as a thermodynamic favored process and supports the HfTaO superstructure as a thermodynamically stable phase.

3. Synthesis of HfTaO superstructure through sintering.

Another approach to form HfTaO superstructures has been conducted. Monoclinic HfO₂ powders and orthorhombic Ta_2O_5 powders were mixed with a mole ratio of 6:1. The mixed powders were cold pressed with a 300MPa pressure and then pressureless sintered at 1650°C for 24 hours. After sintering, the mixed powders were taken out as a bulk ceramic (Fig.5). The XRD investigation indicates that the ceramic is pure HfTaO superstructure.



4. Crystallography of HfTaO superstructure formation.

As mentioned above, the synthesis of HfTaO superstructure through either oxidation of Hf-Ta alloy or through the sintering of mixed oxides, the initial HfO₂ is in monoclinic form, which is stable from room temperature through 1820°C [1]. However, in the crystal structure of the HfTaO superstructure, the HfO₂ is arranged in a cubic form after alloying with Ta oxide. The ready alloying of the Hf and Ta oxides indicates that the HfTaO superstructure can accommodate the excess cations and O^{2-} anions involved in the mixing. A model regarding the similar ZrNbO

crystal structure can shed some light on this mixing process. [3]. Since the cubic HfO_2 possesses a fluorite structure, the cations and anions can be represented by layered arrangements, where excess cations can substitute easily, which is true for Ta substituting for Hf;, however, in the O layer, excess O^{2-} anions need to be arranged properly. This leads to the original square mesh arrangement of O^{2-} anions being transformed into in plane close packed arrangements, which can accommodate the excess O^{2-} (Fig. 6) and yields an overall incommensurate structure..

5. Refractory properties of HfTaO superstructures.

As a material intended to be used at high temperature, some refractory properties are of particular interest. The superstructure is observed to remain stable above 1810° C under torch exposure. The superstructure did not melt or transform after exposure. Moreover, the specific heat of HfTaO at 1650°C was measured as $0.6358 \text{ J/g}^{-1} \cdot \text{K}^{-1}$, which is smaller than that of ZrO₂ (0.6675 J/g⁻¹·K⁻¹). The lower specific heat indicates a lower thermal conductivity. For the HfTaO superstructure, the incommensurate structure illustrated in figure 6 offers a lower thermal conductivity than the periodic ZrO₂ crystal. Since ZrO₂ is a widely used thermal barrier coating, the superstructure has a potential to be a new thermal barrier coating material.

Future Plans

- Determine the detailed crystal structure of HfTaO superstructure.
- Quantify the thermal conductivity and melting point of HfTaO superstructure.
- Relate the crystal structure to the low thermal conductivity of the HfTaO superstructure.
- Verify the oxidation-resistant properties of superstructures with TGA and construct an oxidation kinetics model for the Hf-Ta alloys.
- Explore the oxidation process in other systems composed with Group IV elements (Ti, Zr, Hf) and their β -stabilizer.

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Tailoring Charge Transport and Magnetism in Complex Half-Heusler/Full-Heusler Nanocomposites

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Program Scope

This project exploits (1) the facile co-crystallization of the half-Heusler (HH) and full-Heusler (FH) structures, (2) the high coherency and stability of the HH/FH interfaces, and (3) the solid-state inter-conversion between HH and FH structures through local atomic diffusion, to investigate, for selected compositions of the HH and FH phases, the effect of size, dimensionality, dispersion and volume fraction of FH nanostructures on the electronic, phonon and magnetic behavior of the resulting HH/FH nanocomposites. Our goal is to identify and control key material and growth parameters governing phase formation, microstructural evolution, and to understand the mechanism by which these changes of the internal structure modify the material's performance. To elucidate the mechanism by which the FH nanostructures regulate electronic charge transport and induce ferromagnetism within non-magnetic and magnetic semiconducting HH matrices, suitable series of HH/0D-FH and HH/2D-FH nanocomposites will be fabricated using synthesis conditions suggested by theoretical calculations of the formation energy and stability of various FH phases (varying M) in HH matrices with known chemical composition. The structure of the HH/FH interfaces (size, chemical composition, volume fraction and dispersion) will be investigated along with the evaluation of the electronic (carrier density, mobility, thermopower, electrical conductivity, effective mass), thermal and magnetic (susceptibility, magnetization etc.) properties of the resulting HH/FH nanocomposites.

Recent Progress

During the first three years of this research program, we successfully established that nanocomposites consisting of a HH TNi(Co)Sn(Sb) (T = Ti, Zr, Hf) matrix and coherent FH nanoinclusions can be fabricated by (1) co-nucleation of HH and FH phases during a solid-state reaction of the elements at high temperature or (2) solid-state diffusion of elemental Ni or Co into vacant atomic sites within the crystal lattice of the HH matrix [1-14]. The effect of synthesis and processing methods on the microstructure and electronic transport of bulk nanostructured half-Heusler phases was investigated along with the theoretical investigation of the formation of full-Heusler precipitates in (TiZrHf)NiSn half-Heusler matrix. Theoretical calculations of the HH — FH phase diagram indicate that both phases are very stable up to above 1400 K with minimal solubility between them [2]. In addition, we have also initiated a novel approach for fast design and energy efficient fabrication and characterization of a wide range of technologically important earth-abundant copper-metal-chalcogenide, $Cu(M^{n+})_{3/n}Q_2$ (Q = Se, Te) materials using a synergistic iterative combination of predictive theory and innovative synthesis strategies [3,5].



0.1) nanocomposites. (A) Powder X-ray diffraction patterns, (B) Low magnification TEM image of the sample with x = 0.04, (C) High magnification image of a typical FH nanostructure from the sample with x = 0.04, (D) Low magnification TEM image of the sample with x = 0.1.

The thermoelectric behavior of n-type Sb-doped full-Heusler half-Heusler (HH) _ (FH) nanocomposites with general composition $Ti_{0.1}Zr_{0.9}Ni_{1+x}Sn_{0.975}Sb_{0.025}$ (x = 0, 0.02, 0.04, 0.1) was investigated in the temperature range from 300 775K. Samples used to for structural characterization and transport measurements were obtained through solid-state reaction of high purity elements at 950 °C and densification of the resulting polycrystalline powders using a uniaxial hot press. X-ray diffraction study of the powder samples suggested the formation of single-phase HH alloys regardless of the Ni concentration (x value). However, high-resolution transmission electron microscopy investigation revealed the presence of spherical nanoprecipitates with a broad size distribution coherently embedded inside the HH matrix (Figure 1). The size range and dispersion

of the precipitates depend on the concentration of Ni in the starting mixture. Well-dispersed nanoprecipitates with size ranging from 5 nm to 50 nm are observed in the nanocomposite with x = 0.04, while severe agglomeration of large precipitates (>50 nm) is observed in samples with x = 0.1. Hall Effect measurements of various samples indicate the carrier concentration within the Sb-doped HH matrix remains nearly constant ($\sim 7 \times 10^{20}$ cm⁻³) for samples with x = 0.02 and x = 0.04, whereas a significant increase of the carrier concentration to $\sim 9 \times 10^{20}$ cm⁻³ is observed for the sample with x = 0.1. Interestingly, only a marginal change in thermopower value is observed for various samples despite the large difference in the carrier density. In addition, the carrier mobility remains constant up to x = 0.04 suggesting that the small nanoprecipitates in these samples do not disrupt electronic transport within the matrix. Results of this work are reported in a manuscript published in *Dalton Transactions* [1].

2) Ab Initio study of nano-structured Half-Heusler alloys

Experimental results have shown that FH nano-inclusions coherently integrated into the matrix HH material result in enhanced ZT. This effect is attributed to energy filtering effects that occur at the HH/FH grain boundaries as well as moderate reductions in thermal conductivity by nano-inclusion phonon scattering. Using *Ab Initio* calculations, in combination with a cluster expansion, we have investigated the stability of FH structures in the HH matrix and create a thermodynamic pseudo-binary phase diagram for MNiSn-MNi₂Sn compositions. This was accomplished using the "Cluster Assisted Statistical Mechanics" or CASM, program developed
by Van der Ven group's. We were able to create using first principles calculations a temperaturecomposition thermodynamic phase diagram of the TiNiSn- TiNi₂Sn system (Figure 2).



creates symmetrically The software unique arrangements of atoms along the concentration range of HH to FH structure. Density functional theory as implemented in the Vienna Ab initio Simulation Package (VASP) is then used to calculate the formation energies of the configurations along the composition range. In this calculation of the TiNiSn-TiNi₂Sn system, forty configurations were considered. The formation energies are used in a cluster expansion that results in an effective Hamiltonian able to predict the formation energy of any configuration in the composition range. Using a Monte Carlo simulation the behavior of the system at non-zero temperatures is found and the resulting thermodynamic phase diagram is found (Figure 2). The results show a large miscibility gap between the HH and FH

compounds [2]. This is in agreement with experiments, which confirm that the formation of nano-inclusions is preferred over a solid solution mixture. Detailed calculations of the stability of HH/FH and coarsening of the FH phases at high temperatures are in progress.

3) Rapid Direct Conversion of Cu_{2-x}Se to CuAgSe Nanoplatelets via Ions Exchange



Figure 3: Above: HRTEM images of the Cu_{2-x} Se nanoplatelet template and the final CuAgSe nanoplatelets, Below: EDAX of NPs made with Ag:Se ratio of 0.67.

The use of template nanostructures for the creation of photovoltaic and thermoelectric semiconductors is becoming a quickly expanding synthesis strategy. In this work we report a simple two-step process enabling the formation of ternary CuAgSe nanoplatelets with a great degree of control over the composition and shape. Starting with hexagonal nanoplatelets of cubic Cu_{2-x}Se, ternary CuAgSe nanoplatelets were generated through a rapid ion exchange reaction at 300 K using AgNO₃ solution. The Cu_{2-x}Se nanoplatelet template and the final CuAgSe nanoplatelets were analyzed by

electron microscopy and X-ray diffraction (XRD). It was found that both the low temperature pseudotetragonal and the high temperature cubic forms of CuAgSe phase were created while maintaining the morphology of $Cu_{2-x}Se$ nanoplatelet template. Thermal and electronic transport measurements of hot-pressed pellets of the synthesized CuAgSe nanoplatelets showed a drastic reduction in the thermal conductivity and a sharp transition

from n-type (S = -45 μ V/K) to p-type (S = +200 μ V/K) semiconducting behavior upon heating above the structural transition from the low temperature orthorhombic to the high temperature super-ionic cubic phase. This simple reaction process utilizing a template nanostructure matrix represents an energy efficient, cost-efficient, and versatile strategy to create interesting materials with lower defect density and superior thermoelectric performance [5].

4) Topochemical Solid-State Reactivity: Redox-Induced Direct Structural Transformation from CuSe₂ to CuInSe₂

CuInSe₂ and its solid solution with other trivalent metals (M) have emerged as technologically significant device materials with applications in photovoltaics, thermoelectric, nonlinear optics, etc. However, the complex chemical composition and large tolerance of the CuMSe₂ structure to a wide range of off-stoichiometry generally lead to the formation of undesirable impurity binary phases and electronic defects during fabrication starting from elements. In this work, we demonstrate a simple and elegant strategy for the synthesis of CuInSe₂ with improved control over the chemical composition. The reaction proceeds via a redox induced phase transformation of the line compound copper



Figure 4: Schematic illustration of the proposed mechanism of the redox-induced direct solid-state transformation of CuSe₂ pyrite structure into CuInSe₂ sphalerite structure and TEM image of the 50% CuSe₂/50% CuInSe₂ nanocomposite.

diselenide (CuSe₂) upon incremental addition of elemental indium. Taking into consideration the chemical and structural similarity between CuSe₂ and CuInSe₂, we demonstrate the stepwise direct conversion of the structural template CuSe₂ into $(1-x)CuSe_2/xCuInSe_2$ nanocomposites without the formation of undesirable binary or ternary indium phases. Through X-ray diffraction and transmission electron microscopy it is observed that the structural template provided by CuSe₂ serves as pathway for the formation of CuInSe₂ particles in the size range of 5 to 50 nm [3].

Future Plans

(1) Synthesis, structural characterization and electronic and magnetic properties of TNi(Co)Sn/T(NiM)Sn(Sb) [HH(1-x)/0D-FH(x)] nanocomposites; (2) Theoretical predictions of temperature-composition phase diagram of TNiSn/T(NiM)Sn (HH/FH) systems; (3) Investigation of the mechanism and kinetics of phase transformations in TNiSn/T(NiM)Sn using temperature HH(1-x)/FH(x) nanocomposites dependent X-ray diffraction of TNiSn/T(NiM)Sn HH(1-x)/FH(x) nanocomposites annealed at various temperatures and quenching, (4) Investigation of the dependence of bulk free energies and M (Cr-Zn) diffusion coefficients on HH(1-x)/FH(x) composition, and (5) Continuum simulations of precipitation kinetics and precipitate coarsening in HH(1-x)/0D-FH(x) composites.

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New optoplasmonic materials for next generation energy systems

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Program Scope

Optoplasmonic materials are metallo-dielectric hybrid structures that combine metallic and dielectric components into defined geometries in which plasmonic and photonic modes synergistically interact. These beneficial interactions can be harnessed by integrating plasmonic nanoantennas into photonic environments generated, for instance, by discrete optical resonators or extended systems of diffractively coupled nanoparticles (Figure 1). Optoplasmonic structures facilitate photonic-plasmonic mode coupling and offer degrees of freedom for creating optical fields with predefined amplitude and phase in space and time that are absent in conventional photonic or plasmonic structures. Synergistic electromagnetic interactions between plasmonic nanostructructures localized in the near-field of photonic resonators offers tremendous potential to address long standing limitations of both metallic plasmonic and dielectric photonic resonators.¹ Potential applications include efficient waveguides that transfer energy between nanoscale hot-spots efficiently, all-optical frequency multiplexers and demultiplexers,² and the next generation of metasurfaces with higher compositional complexity. The realization of hybrid materials and structures that contain metallic nanoantennas and photonic resonators in sufficiently synergistic well defined geometries to utilize the



Figure 1: Examples of optoplasmonic structures. SEM images (left) and electromgnetic simulations of the field distribution (right) are shown. Top: Discrete optoplasmonic structure containing a whispering gallery mode resonator surrounded by pillars carrying gold antennas. Bottom: Section of an extended array containing 300 TiO2 nanoparticles and nm clusters 60 nm gold of nanoparticles pre-defined at locations.

electromagnetic interactions remains, however, challenging from a fabrication perspective as it requires the integration of two components (metallic and dielectric structures) of very different size into intricate geometries. The scope of this project is to develop scalable fabrication strategies that allow the experimental realization of optoplasmonic materials of well defined geometry that can utilize synergistic interactions between photonic and plasmonic resonators in a rational way and to elucidate the underlying electromagnetic working principles of these new materials by systematic experimental and theoretical characterization.

Recent Progress

To address the fabrication challenges associated with optoplasmonic materials we have developed template guided self-assembly approaches that allow the fabrication of two optoplasmonic structures: Optopplasmonic hybrid nanoparticle arrays and discrete optoplasmonic resonators that contain both whispering gallery mode resonators and plasmonic antennas.

We have demonstrated that template guided self-assembly approaches facilitate the integration of electromagnetically strongly coupled metallic nanoparticles and dielectric (or semiconductor) nanoparticles at separate, pre-defined locations. In the first step of the assembly procedure nanoparticle assembly sites are created through a lithographic technique electron beam fabrication (e.g. lithography). In the second step these sites are charged positively through incubation with polylysine, and in the last step negatively charged colloidal nanoparticles are immobilized and assembled into clusters on positively charged assembly sites through a charge-mediated assembly process. While electron beam lithography makes it possible to define the separation, Λ , between



Figure 2: Scheme of template-guided selfassembly of extended optoplasmonic arrays. (a) Regular pattern of wells with diameters D1 and D2 (D1 > D2) is created through EBL in a PMMA layer to generate (b) a regular mask of assembly sites with two different diameters. The center-to-center separation in the D1 and D2 subarrays is Λ . (c) Dragging of a suspension of TiO_2 nanoparticles with diameters too large to bind to D2 across the surface results in (d) an immobilization of TiO₂ nanoparticles onto D1 sites. (e) Smaller Au nanoparticles are assembled onto vacant D2 binding sites from a colloidal solution. (f) After PMMA lift-off, the final optoplasmonic array is released.

individual assembly sites on the tens to hundreds of nanometer length scale, the number of nanoparticles on the sites, their separation and the morphology of the assembly are determined by the size and shape of the binding site and the assembly conditions. We have shown that the interparticle separation in the nanoparticle clusters on the assembly sites can be systematically varied on lengths scales of a few nanometers and below through choice of the nanoparticle ligands and buffer conditions. Through combination of top-down and chemical assembly driven bottom-up fabrication, template guided assembly strategies achieve control over interparticle separations ranging from truly nanoscale separation to photonic length scales. The advantages of template guided assembly strategies for generating multiscale *E*-field enhancements in noble metal nanoparticle cluster arrays (NCAs) are well documented.³ What is relevant from an optoplasmonic perspective is that the template guided self-assembly also facilitates the selective binding of particles of different compositions at pre-defined lattice sites, provided these particles also differ in their sizes. Of course, the same strategy can also be applied to arrange particles of identical chemical composition but different sizes (and thus resonance conditions) in pre-defined morphologies.

The underlying strategy is schematically outlined in Figure 2 for an example in which (large) TiO₂ nanoparticles are combined with clusters of (small) Au nanoparticles. First, two different binding sites are patterned in the electron beam resist. Then, the larger TiO₂ nanoparticles are immobilized on the large diameter binding sites, leaving the smalldiameter binding sites vacant for the binding of Au nanoparticles in a subsequent binding step. Figure 3 contains exemplary SEM images of different arrays obtained from 60 nm Au nanoparticles and 250 nm diameter TiO₂ nanoparticles with binding sites containing diameters of D2 = 140 nm and D1= 270 nm, respectively. The resulting arrays



Figure 3. SEM images of 2D arrays generated through template guided self-assembly of 250 nm TiO_2 nanoparticles and 60 nm Au nanoparticles. (a) Section of optoplasmonic array. (b) Complete optoplasmonic array with 20×20 TiO₂ nanoparticles. (c) Side-view (30° tilt angle) of optoplasmonic array section. d) Section of TiO₂ nanoparticle array. (e) Section of Au nanoparticle cluster array. Λ is 1000 nm in (a) – (e). Scale bars are 500 nm in (a) and (c) – (e), and 2 µm in (b).

show a successful localization of TiO_2 nanoparticles and Au nanoparticle cluster to distinct lattice sites. The optical resonances of these hybrid arrays were investigated in detail and showed clear evidence for synergistic electromagnetic coupling.

An alternative strategy to position metallic antennas into a well defined photonic environment relies on placing metal nanostructures in direct vicinity of whispering gallery mode

resonators that provide a rich spectrum of sharp spectral features. The particular challenge for the realization experimental of these with defined structures optical responses is the requirement to position one or multiple plasmonic antennas at defined locations in the evanescent field of an individual microsphere resonator or network of microsphere resonators. A chemical or charge mediated direct attachment of nanoparticles to the resonator is limited in scope for this purpose, as these strategies do not provide control over the location and, in the case of anisotropic nanoparticles and assemblies, orientation of the



Figure 4. (a) Schematic illustration of the fabrication process for optoplasmonic structures. Noble metal nanoparticle tipped pillars were fabricated through electron beam lithography followed by reactive ion etching. The generated cavities were filled with microspheres by convective self-assembly of an aqueous solution of PS microspheres. (b-i) SEM images of diverse optoplasmonic structures generated through templateguided self-assembly. Scale bars in all images are 1 μ m.

plasmonic components. Furthermore, it is difficult to create gap antennas in a controlled fashion

by nanoparticle attachment, and the separation between the antenna and the dielectric resonator can also not be systematically varied. Instead, we developed the template guided self-assembly process outlined in Figure 4, which positions plasmonic antennas supported by dielectric posts into the equatorial plane of the whispering gallery mode resonator for maximum coupling efficiency. We are currently investigating the ability of these structures to guide light over long distances and subsequently relocalize it into plasmonic hot-spots. As shown in Figure 5, the preliminary results are encouraging and show emission of reporter dyes from antennas localized along the optoplasmonic chain. This is an important accomplishment as it proves that optical functionalities such as long range energy transfer. multiplexing and demultiplexing based on optoplasmonic geometries are feasible.

We are currently expanding this design approach to silicon resonators with metal nanoparticles at defined locations. So far, we were able to demonstrate a strong enhancement of



Figure 5: Fluorescence images of an optoplasmonic chain whose gold antennas are functionalized with Cy5. The detected fluorescence intensity 2, 4, 6 and 8 μ m away from the quantum dot covered bead that acts as excitation source confirms long distance energy transfer and relocalization at the nanoantennas.

both near-field and radiative rates when compared with the isolated building blocks.

Future Plans

There is an increasing interest in the materials science community in non-metallic materials for plasmonic applications.⁴ Conducting oxides, germanides, nitrides, silicides, to name only a few, have all shown great potentials as plasmonic materials and are – different than metals – completely CMOS compatible and much cheaper. In metal plasmonics we have learned that the ability to pattern nanoparticles in discrete arrays provides a significant gain in functionality due to collective resonances. In the future we intend to develop a new class of optoplasmonic materials that incorporates non-metallic plasmonic materials. This research builds immediately on our recent accomplishments of patterning metallic and dielectric nanoparticles and will result in a completely new class of metasurfaces that can provide exquisite control over light fields in ultra-thin materials.

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Using Interfaces to Create Strongly-Coupled Magnetic-Ferroelectrics

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I. PROGRAMSCOPE

Our objective is to create a ferromagnetic ferroelectric that can be deterministically switched between symmetry equivalent states using an electric field. Until recently, the electric-field switching of a magnetization between 180° symmetry equivalent states had not been demonstrated in any material.¹ The required coupling between ferroelectric and ferromagnetic domains allowing such switching is a missing feature in most multiferroics and is key to advancing the field both scientifically and technologically. Starting at the level of electrons and atoms our goal is to rationally design complex oxide heterostructures and interface-materials with this targeted emergent behavior. Using a combination of symmetry arguments and first-principles calculations to explore the connection between structural distortions and ferroelectricity in the perovskite family of materials, we have predicted electrical control of magnetism in the hexagonal rare earth ferrites². These realizations are created with atomic-layer precision, microscopically interogated to see if there are competing mechanisms to the intended realization, and finally their macroscopic properties are measured. Here we will develop the scientific ideas and experimental tools necessary to apply this design paradigm to the creation of multiferroics with unprecedented coupling between ferroelectric and magnetic order parameters.

II. RECENT PROGRESS

Over the last 3 years our team has been able to investigate strongly coupled magnetic ferroelectrics in a comprehensive way—from materials-by-design theory to state-of-the-art synthesis and characterization. Our work has overcome and pushed the multiferroic field beyond the limiting notion that it is best to start with a material that displays ferromagnetism, and devise a way to induce ferroelectricity or vice-versa. While highly successful at creating new multiferroics (materials that are both ferromagnetic and ferroelectric), generally speaking this approach has not led to a widespread solution to the central problem of *strong coupling* between the polarization and the magnetism. The reason is believed to be due to the common origin of the ferroelectricity in these materials (small cation displacements such as those in the prototypical perovskite ferroelectric BaTiO₃).

Our team has invented new mechanisms for multiferroics, which provide strong coupling between polarization and magnetism. Specifically, multiferroics based on spin-phonon coupling,³ rotation-driven multiferroicity,^{4,5} and novel geometric multiferroics.⁶ Importantly, the latter two of these mechanisms enable the deterministic switching of magnetism by an applied electric field,^{12,7} which is key to the application of multiferroics to future device technologies. In addition to coming up with these strongly coupled magnetic ferroelectric ideas in this program,^{3-6,8-10} we have also made and studied these materials to compare them to expectations from theory.¹¹⁻¹⁹

Overall, our team has discovered new frontiers for strongly coupled multiferroics in thin film form. Our DOE-supported work has led to 22 publications in peer-reviewed journals.^{3-6,8-} Below we highlight our most recent breakthrough in the field of multiferroics that builds upon our understanding of related phases.^{6,11,15,17-19}

 $LuFe_2O_4$ was reported to be simultaneously ferrimagnetic and ferroelectric at 250 K, the highest temperature of any known material.²⁷ Although its ferrimagnetic ordering is widely affirmed,²⁸ recent studies from multiple groups find that LuFe₂O₄ is not ferroelectric.²⁹⁻³² Interestingly, a robust high-temperature ferroelectric with a closely related structure and chemistry exists: hexagonal LuFeO₃. Although metastable, hexagonal LuFeO₃ has been grown in thin film form by epitaxial stabilization.33-35 Isostructural YMnO₃, it is an improper ferroelectric,^{6,36} where the rumpling of the Lu-O planes and corresponding tilt of the Fe-O trigonal bipyramids lead to geometric ferroelectricity that persists well above room temperature.^{18,35} At low temperature hexagonal LuFeO₃ orders antiferromagnetically (T_N) ; slight canting of the spins gives rise to weak ferromagnetism.^{6,18,35}

We created a new multiferroic through the atomic-layer integration of $LuFe_2O_4$ and $LuFeO_3$ and identify $(LuFeO_3)_9(LuFe_2O_4)_1$ as a strongly magnetically ordered ferroelectric up to 281 K. The claim of a phase that is simultaneously ferroelectric and ferromagnetic (or ferrimagnetic) at room temperature has been made before.³⁷⁻⁴⁰ In contrast to prior reports, however, we corroborated this result using methods that are insensitive to magnetic impurity phases (e.g., neutron diffraction) or electrical leakage (e.g., high-resolution electron microscopy) and also showed how our results are consistent with first-principles calculations.



Fig. 1. HAADF-STEM images of the (a) end members $LuFe_2O_4$ and $LuFeO_3$ and (b) $(LuFeO_3)_m(LuFe_2O_4)_1$ superlattice series for $1 \le m \le 10$. Samples are imaged along the LuFeO_3 $P6_3cm$ [100] zone axis. $LuFe_2O_4$ is imaged down the equivalent zone axis, which due to the primitive unit cell of $LuFe_2O_4$ is the [120] zone axis. Cartoons are shown of the $LuFe_2O_4$ and $LuFeO_3$ crystal structures with lutetium, iron, and oxygen in turquoise, yellow, and brown, respectively.

Figure 1(a) shows the high-angle annular dark field scanning transmission electron microscopy (HAADF-STEM) of the LuFeO₃ and LuFe₂O₄ end-members and Fig. 1(b) the $(LuFeO_3)_m(LuFe_2O_4)_1$ superlattices for m=1 to m=10. The characteristic "up-up-down" pattern of the lutetium atoms in LuFeO₃, which is also observed in LuFeO₃ and the hexagonal

manganites⁴²⁻⁴⁴ is evident and reflects the polar nature of these superlattices. The polarization monotonically tracks the magnitude of this lutetium trimer distortion,⁶ rendering HAADF-STEM a local probe of ferroelectricity. Inspecting the images in Fig. 1, we note that distortions are present in the $(LuFeO_3)_m(LuFe_2O_4)_1$ series for $m \ge 2$.

The measured magnetic properties of the $(LuFeO_3)_m(LuFe_2O_4)_n$ superlattices are displayed in Fig. 2. The shapes of the M-T curves for the superlattices are the same as that of the $LuFe_2O_4$ *M*-*T* curve, suggesting that the magnetization observed in the superlattices likely most is ferrimagnetic of the same kind as In Fig. 2(c), $T_{\rm C}$ is plotted as $LuFe_2O_4$. a function of the fraction of the iron layers that sit in LuFeO₃ layers, /m + 2n. Strikingly, the superlattice transitions are higher than thin films of both of the constituent layers, LuFeO₃ $(T_{\rm N}=147 {\rm K})^{15}$ and $LuFe_2O_4$ $(T_{\rm C}=219 {\rm K}).^{11}$ For the $(LuFeO_3)_m(LuFe_2O_4)_1$ series, the Curie temperature ferromagnetic increases to $T_{\rm C}$ =281 K for *m*=9. The magnetization vs. applied magnetic field (M-H)loops of $(LuFeO_3)_9(LuFe_2O_4)_1$ show that the saturation magnetization remains to ~350 K, suggesting that short-range ferromagnetic fluctuations persist well above room temperature.

The observed enhancement of the magnetic transition temperature and moment shown in Figs. 2(c) and 2(d) could arise from the LuFe₂O₄ matrix



Fig. 2. Magnetic characterization of the $(LuFeO_3)_m(LuFe_2O_4)_n$ superlattices. (a) *M*-*T* curves for a series of $(LuFeO_3)_m(LuFe_2O_4)_1$ superlattices 1 kOe field. cooled in a (b) Saturation of magnetization the $(LuFeO_3)_{0}(LuFe_2O_4)_{1}$ (c) The superlattice. ferromagnetic Curie temperature extracted from the curves in (a). The ferromagnetic Curie temperature reaches a maximum of 281 K for the $(LuFeO_3)_9(LuFe_2O_4)_1$ compound. The total moment per $LuFe_2O_4$ iron atom at 50 K is plotted in (d) assuming the moment of LuFeO₃ remains constant. (e) Average lutetium displacement from HAADF STEM for superlattice layering plotted as a function of the composition for the $(LuFeO_3)_m(LuFe_2O_4)_1$ and $(LuFeO_3)_1(LuFe_2O_4)_n$ series. Ferroelectric distortions are observed in the

samples in Region II where $m_{!(2n+m)} \ge 0.5$, corresponding to $(LuFeO_3)_m(LuFe_2O_4)_1$ superlattices with $m \ge 2$.

incurring structural, stoichiometric or spin-lattice changes when epitaxially integrated with the LuFeO₃ layers. Figure 2 suggests two distinct regions with a separate interplay of these effects: Region I for $0 < \frac{m}{m+2n} < 0.5$ where the T_c saturates at ~250 K and the LuFe₂O₄ moment is constant and Region II for $0.5 \le \frac{m}{m+2n} < 1$ where a further increase of T_c to 281 K is

coupled with an enhanced magnetic moment and the observation of lutetium atomic distortions.

First-principles density functional theory (DFT) calculations were used to probe the

enhanced moment and $T_{\rm C}$ observed in Region II. The ground state of LuFe₂O₄ is an antiferroelectric charge-ordered state, "COI," as shown in Fig. 3(a). The state ferroelectric charge-ordered "COII" as well as non-polar chargeordered "COIII" configurations shown in Figs. 3(b) and 3(c) have energies higher than the COI ground state. The magnetization as a function of temperature for the COI ground state calculated from the Heisenberg spin model is shown in Fig. 3(d). The lowenergy state COII was found to be susceptible to the tri-fold lutetium distortions characteristic of LuFeO₃ (but not observed in the LuFe₂O₄ state in increasing bulk). Artificially the distortion vector, Q, in the COII state monotonically increased the in-plane super-exchange interaction and in turn the magnetic transition $T_{\rm C}$ as shown in Fig. 3(d). While this already suggests that the enhancement of the magnetic transition temperature in the $(LuFeO_3)_m(LuFe_2O_4)_1$ compounds with $m \geq 2$ is attributable to the lutetium distortions borrowed from the LuFeO₃ layers, we also calculated the structure of the m=1 and m=3 superlattices directly.

In contrast to LuFe₂O₄, DFT calculations of the m=1 superlattice found the most stable configuration corresponds to a "Fe³⁺-doped" COII-type configuration with a 2:1 ratio between Fe³⁺ and Fe²⁺ in each layer. In the Fe³⁺-doped superlattices, the net magnetization is due to ferromagnetically aligned Fe²⁺ ions



Fig. 3. First-principles calculations of the $LuFe_2O_4$ spin configuration. Monoclinic structures of $LuFe_2O_4$ for Fe^{2+}/Fe^{3+} (a) antiferroelectric chargeordered (CO) state (COI), (b) ferroelectric CO state (COII), (c) non-polar CO state (COIII), respectively. The energy of the structure is given in meV per formula unit for a range of Hubbard U values. (d) Calculated saturation magnetization per iron as a function of temperature for the ground state antiferroelectric COI state shown in (a). The magnetization saturates at ~0.4 $\mu_{\rm B}/{\rm Fe}$. (e) Calculated saturation magnetization per iron as a function of temperature for the ferroelectric COII state shown in (b). Q represents the amplitude of the atomic distortions from the high symmetry $R^{3}m$ structure. The magnetic transition temperature increases with the magnitude of the structural distortion associated with the ferroelectric state.

located at the centre of Fe^{3+} hexagons and the magnetization observed is higher than in the COII structure. The *m*=3 superlattice in the "Fe³⁺-doped" state also displays charged-ferroelectric domain walls: the polarization aligns "tail-to-tail" at the LuFe₂O₄ bilayers and has a corresponding "head-to-head" domain wall in the LuFeO₃ block. Plotting the density of states at each layer, we observe that electrons migrate from the Fe³⁺-doped LuFe O₄ layers to screen the excess of bound charges at these domain walls resulting in a further increase in the



Fig. 4. Ferroelectric domain structure of $(LuFeO_3)_m(LuFe_2O_4)_1$ superlattices. ³⁴(a) Firstprinciples calculations of the $(LuFeO_3)_3(LuFe_2O_4)_1$ superlattice found that the "Fe doped", structure is the lowest in energy, where the $LuFe_2O_4$ layers are composed of a 2:1 ratio of Fe to Fe²⁺ cations as pictured in yellow and green, respectively. This structure aligns tail-to-tail domain walls at the $LuFe_2O_4$ layer positions. Lutetium atoms contributing to "up" polarization are plotted in turquoise and lutetium atoms contributing to "down" polarization are plotted in red. (b) and (c) show the experimental HAADF-STEM images of the $(LuFeO_3)_7(LuFe_2O_4)_1$ and $(LuFeO_3)_9(LuFe_2O_4)_1$, respectively. The images are colored according to the measured polarity. Tail-to-tail domain walls are observed at the $LuFe_2O_4$ layer positions.

magnetization.

HAADF-STEM images of the m=7 and m=9 superlattices are shown in Figs. 4(b) and 4(c). We observe a clear repetition of the tail-to-tail domain walls at the LuFe₂O₄ bilayers and meandering head-to-head walls in the LuFeO₃ blocks corresponding to the predicted structure for higher *m*. This domain architecture is not observed in the lower *m* superlattices, perhaps due to the stability of the COII structure for these layerings.

In summary, we have synthesized a series of compounds, $(LuFeO_3)_m(LuFe_2O_4)_1$ with $m \ge 2$, in which ferroelectricity enhances magnetism at all relevant length scales. The room-temperature ferroelectric polar distortions of the Lu-O planes enhance the ferromagnetic (or ferrimagnetic) transition temperature in the LuFe₂O₄ layers. This results in a structure that is strongly magnetically ordered with a T_C near room temperature that retains ferromagnetic fluctuations above room temperature. Moreover, precise atomic-layer engineering of the tail-to-tail domain walls to the LuFe₂O₄ further increases the magnetic moment.

III. FUTURE PLANS

Our renewal project has two research objectives, both of which relate to the better understanding of a new class of $A_{n+1}B_nO_{3n+1}$ Ruddlesden-Popper phases possessing a ferroic instability. Our first-principles calculations indicate that the ferroelectric vs. antiferroelectric alignment of neighboring polar slabs in $Sr_{n+1}Ti_nO_{3n+1}$ is nearly energetically degenerate, The

first research objective of our project is to manipulate control parameters to create novel functionalities in a new family of ferroics. The near degeneracy between ferroelectric vs. antiferroelectric alignment of neighboring polar slabs in $Sr_{n+1}Ti_nO_{3n+1}$ begs the question of whether relaxor ferroelectricity can be created and systematically studied in this system without begs the question of the chemical disorder^{46,47} or free surfaces⁴⁸ that are present in all known relaxor ferroelectrics. Our studies will go beyond strained $Sr_{n+1}Ti_nO_{3n+1}$ by considering the site-specific incorporation of species that lead to ferroelectric instabilities without strain, e.g., the introduction of calcium, barium, and lead into this general family to form ordered $(Ca,Sr,Ba,Pb)_{n+1}Ti_nO_{3n+1}$ phases. These hypothetical phases containing calcium, barium, and lead are metastable. Nonetheless, we have already demonstrated that one such phase, BaSr₂Ti₂O₇, can be grown by MBE, making it likely that we will be able to synthesize these novel phases. Intriguingly, our first-principles calculations reveal a nearly isotropic in-plane polarization of Pb₂TiO₄ under appropriate biaxial strain (about 0.7%).⁵⁰ This unusual energetic landscape is tantalizing in that it might give rise to an electrical analog of ferromagnetic resonance. Guided by theory, we will explore this and other unusual physical properties of these ordered (Ca,Sr,Ba,Pb)_{n+1}Ti_nO_{3n+1} phases. Our second research objective is to better understand the role of defects in these structures. The extremely low dielectric losses exhibited by the strained $Sr_{n+1}Ti_nO_{3n+1}$ phases that we have studied to date lead us to hypothesize that these Ruddlesden-Popper structures contain fewer point defects than their perovskite analogs.⁵¹ But is this true? We will assess this through experiments on ordered $(Ca,Sr,Ba,Pb)_{n+1}Ti_nO_{3n+1}$ films vs. their perovskite analogs, $SrTiO_3$, $BaTiO_3$, and $PbTiO_3$ analyzed by scanning transmission electron microscopy (STEM) utilizing a new mixed-mode pixel array detector capable of imaging polarity, strain fields, and contrast and dechanneling from vacancies and interstitials. We will also study the defects by positron annihilation spectroscopy, phonon spectroscopy, and the frequency dependence of dielectric loss (especially in the GHz frequency regime). Theory is an integral part of interpreting these experiments.

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In Situ Thermodynamics and Kinetics of Mixed-Valence Inorganic Crystal Formation

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Program Scope

We are developing efficient routes to discover inorganic materials that straddle the semiconducting regime while we map their energy landscape experimentally and computationally. Our ability to move through chemical and thermal space in situ is accomplished by our in-house capillary diffraction setup, shown schematically in Figure 1. We are free to run reactions of any duration, which is a distinct departure from user facilities. Gas flow capability will allow us to conduct synthesis and metathesis reactions that move this beyond an observational study and into the realm of control. Concurrently, we will establish sets of best practices for utilizing computational genome-based tools for high-throughput prediction of enthalpies to guide synthesis.

representative systems As we will test hypotheses of phase formation in light-absorbing semiconductors in the Fe-Si-S and Ba-Fe-S systems. First, we seek to verify whether new non-magnetic phases exist in this phase space that contain FeS_6 octahedra. Second, we believe that valence stability in these phases, which is known to be a serious problem in pyrite FeS₂, [1] is highly dependent on the crystal structure of each individual phase, and not mandatory for the Fe^{2+} ion. We will test this hypothesis by strong reduction and sulfidization in situ. This route to investigate valence stability has applications in many systems, notably chalcogenide semiconductors and transparent conducting oxides. We will conduct gas flow reactions to probe the thermodynamics and kinetics of valence stability. Current theory is outmatched by this problem and will be informed by our experiments.



Figure 1. Schematic of our in-house setup for encapsulated materials synthesis with transmission X-ray diffraction.

Our experimental efforts interface with computation on two fronts. First, exploratory synthesis parallels the genetic-algorithm searches by programs such as USPEX, [2] which offloads enthalpy calculations to DFT. Our preliminary work has shown us that this approach, while valuable in some systems, has notable drawbacks for transition metal compounds and those with relatively flat energy landscapes. Our attention now turns to prediction of *which systems* will benefit from this approach, rather than individual phases.. Second, big-data genomic

approaches such as the Materials Project [3] provide a new and convenient framework to track and compare enthalpy values during reactions and find routes to new compounds. The scope of this work is to understand how to efficiently leverage the vast amount of thermodynamic data that is available. In this sense, finding the proper reagents for a synthesis is a genomic task, and so is uncovering fertile ground for the genetic algorithm approach.

Recent Progress

Two in situ furnaces are necessary for this work. A uniform "oven" type furnace that slides over a capillary, and a fast-heating furnace that permits gas flow through the capillary. First, we optimized the geometry of our existing oven furnace to remove scattering contributions from the thermal insulation and the Soller slits, by trimming and masking the insulation and machining a custom anti-scatter slit. The resulting "empty" run is shown in Figure 2, with multiple steps in the process shown. We now have a clean background, with substantially improved signal-to-noise and clear resolution of even very minor phases that nucleate in our in situ reactions. Second, we have begun machining a Chupas-style





flow furnace for our in-house diffractometer. [4] This is not a straightforward task since the gap between the goniometer mount and the sample is quite short in our instrument, which necessitated a redesign of the gas inlet block.

In our previous work doing in situ characterization at beamlines, [5] the inability to efficiently program and log the in situ reaction temperature impaired our ability to monitor long

experiments, or those with complex or fast heating and cooling steps. We have designed an experimental suite to program the furnace setpoint, log temperature, and collect diffraction data simultaneously on the fly on our in-house system. We expect that these capabilities will be extended to any beamlines (e.g. APS 17-BM) where a similar furnace is used but not yet interfaced with an automatic logging system.

Our first synthetic work on the Fe—Si—S system has shown very strong kinetic effects, which is an encouraging signature of multiple synthetic routes to new phases in this and related systems. For the target phase Fe_2SiS_4 , it may be expected that heating





to relatively high temperatures, such as 600°C, would lead to formation of the thermodynamic ground state. Instead, we found that SiS_2 forms quickly and is so kinetically sluggish that it prevents formation of a stoichiometric amount of Fe_2SiS_4 , resulting in the diffraction pattern in Figure 3. Instead, the prereaction of Fe + 2S to form FeS₂, followed by subsequent reaction by Si, should be an effective route to pure Fe_2SiS_4 . [6]

Future Plans

To search for new phases and verify the predicted ternary phase diagram from calculated enthalpies, we will conduct two investigations of the Fe-Si-S system, with the ternary phase diagram shown in Figure 4. First, a "classical" equilibrium study with long annealing times and and slow cooling will be performed in situ. Second, a kinetic phase diagram starting from FeS₂, FeS_{1- δ}, and elemental Si will show how these phases respond without the fast initial formation of the parasitic phase SiS₂. This technique of selectively flattening the energy landscape will be examined starting from other points on the edges of the ternary space (e.g. FeSi, FeSi₂, etc.). Probing for new phases will occur in at least 8 composition points, shown as (+) marks in Figure 4. Our method of in situ synthesis is also vastly more informative than experiments that search for metastable compounds by quenching reactions for post-mortem characterization.



Our preliminary computational work began with the intent to predict new target compounds with genetic algorithms. We have since found that the computation is actually significantly *slower* than experiment in the current implementation. This is an opportunity for our group to use our synthetic expertise to identify model synthetic systems where the predictive approach can be validated, before extending it to unknown systems. While the potential for USPEX searches to contribute to synthesis remains, there is no consensus on how accurate the enthalpy calculations must be to return value to the process, or even if Δ H alone constrains the process. Fe₂SiS₄ and Fe₇S₈, among others, are calculated to be as much as 0.5 eV above the hull (unstable), but these phases are in fact easily synthesized. This may be due to entropic or kinetic contributions or errors in the DFT-calculated enthalpy. In any case, our experimental calorimetric and isothermal in situ kinetic data will answer these questions and define the next steps in computationally-assisted synthesis.

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Discovery and Crystal Growth of New Oxide Phases from Metal Fluxes

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Program Scope

Discovery and growth of crystalline materials is one of the key areas in materials research. New materials, and engineering of their properties, have produced tremendous progress; and the search for new materials with novel properties remains an ongoing activity. Of the many oxide single crystal growth methods, flux growth has proven to be an excellent method for exploratory synthesis work that also will yield crystals large enough for structural and physical characterization. Using metal fluxes to grow oxide phases produces a unique crystal growth environment, where oxygen is now a minority constituent. The low melting point of certain metal fluxes in use allows low temperature synthesis, and gives access to potentially metastable and hard to crystallize phases. We are investigating single crystal oxide growth from alkaline earth metal fluxes, where the sizable oxygen solubility as well as good solubility of lanthanides is used to discover new phases. The reactivity of the flux can be tailored to provide reducing conditions for oxide growth by using alkaline earth mixtures, or the flux material can also be incorporated into the oxide. Especially the low temperature eutectic mixtures of magnesium with calcium, strontium and barium provide control not only over crystal growth temperatures, but also the reactivity of the flux and its power to reduce lanthanide oxides. Furthermore, alkaline earth metal fluxes have simultaneous solubility for oxides, halides, and chalcogenides, and new multi-anion phases have been synthesized.

Recent Progress

Our research activities resulted in the discovery of new phases in the $Ba_3Ln_2O_5Cl_2$ system, with Ln a lanthanide ion from Sm to Lu. The ferromagnetic semiconductor EuO was investigated further to optimize the crystal growth and control the inclusion of barium into the Eu sublattice. The magnetic properties of a series of crystals were measured.

$Ba_3Ln_2O_5Cl_2$

The alkaline earth metal fluxes are found to have sufficient solubility for halides, allowing the crystallization of new oxyhalide phases. Similar to the recently discovered

oxytelluride, Ba₃Yb₂O₅Te, both systems contain perovskite-like Ba₂Ln₂O₅ double-pyramidal layers.¹ In contrast to Ba₃Yb₂O₅Te, where so far, only the Yb and Lu phases could be synthesized, the Ba₃Ln₂O₅Cl₂ system accommodates a larger range of lanthanides, from Sm to Lu. Here, the lanthanide is on the perovskite B-site, and structurally, it is a highly strained configuration. These layers are separated by BaCl₂ layers, which help to stabilize the perovskite-type layers. The presence of the BaCl₂layers separates the magnetic lanthanides, so that their magnetic behavior is that of a square lattice. Ba₃Gd₂O₂Cl₂ has an antiferromagnetic phase transition at low temperatures, at $T_N=2K$, which is expected to be the highest transition temperature in the series. The structural study is almost complete, and the magnetic susceptibility measurements are in progress.

Europium Oxide, EuO

Among ferromagnetic semiconductors, EuO is one of the first compounds that were discovered, and investigated in detail.² The simple rock-salt structure of EuO makes this material a model compound to study magnetic interactions. In addition, the highly coupled electronic and magnetic interactions give rise to properties that reflect this coupling. For instance, the ferromagnetic order changes the electronic band structure, splitting into spin up and spin down bands.

Crystal growth of EuO is usually performed at high temperatures (>2000C) using excess Eu in sealed tungsten crucibles.³ Here, we demonstrate a low temperature growth method for EuO, using a barium/magnesium flux and Eu₂O₃. The reactivity of the flux is tailored via its Mg content, to reduce Eu₂O₃ to EuO. Single crystal growth is achieved at temperatures below 1000C, with some inclusion of Ba

into the EuO, forming (Eu,Ba)O. The Ba inclusion depends on the Mg content of the flux, with increasing Mg lowering the Ba inclusion.

The system (Eu,Ba)O was investigated for its magnetic properties: susceptibility and M-H loops were measured for all crystals along the [100] direction. The magnetic properties depend linearly on the Ba content, with the ferromagnetic Curie temperature T_c decreasing with increasing Ba content (Figure 2). All crystals showed universal behavior when scaled to a reduced temperature T/T_c and reduced magnetic susceptibility, demonstrating that the magnetic interactions scale linearly with the Ba content. However, the ferromagnetic T_c as determined by

structure

0.10 Barium concentration x in Eu, Ba,O Figure 2: Eu_{1-x}Ba_xO ferromagnetic ordering temperature vs Ba concentration.





Arrott-plots and the high temperature exchange determined from the Weiss constant show that the fluctuations differ at high Ba concentrations. Doping of (Eu,Ba)O was attempted, but so far, all crystals are highly insulating.

Ba_2TeO

A new oxytelluride was synthesized using molten Ba metal flux, with a simple structure closely related to PbFCl.⁴ Ba₂TeO is comprised of alternating inverse PbO-type BaO layers and slightly puckered NaCl-type BaTe layers. The Ba₂O₂-type layer can also be considered as a strongly puckered NaCl-layer, and the structure is a combination of a Ba₂O₂ layer and two BaTe layers (Figure 3). Insulating behavior is observed: an optical band gap of 3eV is found.



Figure 3: (a) Ideal structure of layered BaO and BaTe, (b) structure where the oxygen atoms have moved, and finally (c) the actual structure of Ba_2 TeO with puckered BaTe layers.

SmMg₂Bi₂ and SmMg₂Sb₂

We have grown the new compounds $SmMg_2Sb_2$ and $SmMg_2Bi_2$ as single crystals from a molten flux.⁵ The two crystals contain samarium in the divalent Sm^{2+} state; as determined from magnetic measurements. The electronic properties of these materials show that they are p-type materials with a low electron density, making them potential thermoelectric materials. The synthesis of the materials is performed in a magnetic, electronic and thermal properties have been measured to determine the electronic ground state of the material and to confirm that the valence of Sm is indeed 2+, since the stabilization of divalent samarium in a molten metal flux is unprecedented. The flux was engineered to provide the reducing conditions by adjusting the magnesium content. Understanding how to access Sm^{2+} broadens the availability of chemical constituents in various materials.

Future Plans

$Ba_3Ln_2O_5Cl_2$

The series of lanthanide phases of $Ba_3Ln_2O_5Cl_2$ will be characterized for their magnetic properties. Potentially, magnetic 2-dimensional behavior will be looked for, since the structure

separates $Ba_2Ln_2O_5$ double-pyramidal perovskite-type layers by $BaCl_2$ layers. These phases are reasonably stable in the ambient.

LnOCl, LnOBr

The oxychlorides of lanthanides are used as host materials for optical down conversion and luminescent materials in solid state lighting applications.⁶ However, of the lanthanide series, only a few oxychlorides have been prepared as single crystals. Using alkaline earth fluxes, BaO as oxygen source and FeCl₃ as chlorine source, it was possible to grow, for the first time, single crystals for most of the LnOCl. We plan to investigate DyOCl for its low temperature magnetic properties since crystal field effects may provide an anisotropic g-factor resulting in Ising behavior. Oxybromide growth will be pursued to investigate the phase stability and crystal growth of LnOBr. Optical characterization of these systems is planned.

New flux compositions

New flux compositions with transition elements added are investigated. Recent experiments using Ba/Cu fluxes look promising, where the oxygen solubility is maintained. In addition, a Mg rich flux shows good solubility for phosphorus concurrent with oxygen. In this way, a different route to phosphides is possible that does not use the transitional tin flux. We plan to explore lanthanide oxyphosphide phases, and study their magnetic properties. Extension to arsenic is considered.

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Electrodeposition of Water-Splitting Catalysts and Epitaxial Perovskite Films for Solar Energy Conversion

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Program Scope

In our lab, we have studied the epitaxial electrodeposition of metal oxide thin films onto single-crystal substrates for several years. We recently applied these methods to the production of materials for solar energy conversion. In this presentation we present work on two topics: i) the electrodeposition of water-splitting catalysts for photoelectrochemical cells, and ii) the electrodeposition of epitaxial methylammonium lead iodide perovskite thin films for solid-state photovoltaic cells.

The kinetic bottleneck of electrochemical and photoelectrochemical water splitting is the four-electron oxygen evolution reaction (OER).¹ OER catalysts include transition metal oxides such as RuO₂, IrO₂, PtO₂, MnO₂, and Co₃O₄. Although the most active of these catalysts are the expensive noble metal oxides RuO₂, IrO₂, and PtO₂, there is interest in developing OER catalysts based on earth-abundant metals such as Co.^{2,3} We are interested in understanding the effect that these catalysts have on the interfacial energetics (e.g., barrier height) in photoelectrochemical solar cells.⁴ That is, do they serve simply as innocent catalysts, or do they produce solid-state Schottky barriers?

Methylammonium lead iodide (MAPbI₃) perovskites are efficient light harvesters in photovoltaic solar cells. Since their introduction as a light absorber in TiO_2 -based solar cells in 2009, the conversion efficiency of perovskite-based photovoltaic cells increased from 3.8 to 20.1% in only four years. Although most research on perovskites has focused on producing polycrystalline films by simple and inexpensive solution processing methods, recent results have shown that large-grained materials and single crystals have lower trap densities, longer diffusion lengths, enhanced photoluminescence, and higher photovoltaic conversion efficiency. In addition to producing higher efficiencies, highly ordered samples provide the opportunity to measure the intrinsic electronic and optical properties of the perovskites. An important next step in perovskite research is to grow the material as epitaxial films, in which the out-of-plane and in-plane orientation of the material is controlled by the substrate.

Recent Progress

Water Splitting Catalysts:

Photoelectrochemical water splitting is an intriguing way to convert solar energy into a storable fuel. Electron-hole pairs are generated and separated in the depletion region in a semiconductor electrode, and the carriers are then driven to the electrode surface to oxidize (for n-type semiconductors) or reduce (for p-type semiconductors) water. A thin catalyst layer applied to the semiconductor surface improves the kinetics of electron transfer from the semiconductor to the solution, and protects the semiconductor from photocorrosion and

passivation. A fundamental question in these modified semiconductor electrodes is how this catalyst affects the band bending (and, therefore, the photovoltage) in the semiconductor. We have recently introduced a simple and inexpensive electrodeposition method to produce an efficient n-Si/SiO_x/Co/CoOOH photoanode for the photoelectrochemical oxidation of water to oxygen gas. We also quantitatively analyze the interfacial energetics. We find that the photovoltage is determined by the catalyst, but that the barrier height for thin, inhomogeneous catalyst layers is 0.30 eV larger than the 0.61 eV that has been observed for a solid-state Schottky barrier produced in vacuum.



Figure 1 Photoelectrochemical performance of the n-Si/SiO_x/Co/CoOOH photoanode. a, Linear sweep voltammetry comparing n-Si in the dark (black), p^+ -Si/SiO_x/Co/CoOOH in the dark (blue), and n-Si/SiO_x/Co/CoOOH under 100 mW cm⁻² AM 1.5 irradiation (red) in 1 M KOH at a 10 mV s⁻¹ scan rate. b, Calculated photoresponse of an n-Si/Co Schottky cell with a barrier height of 0.61 eV (black), and measured photoresponse of the n-Si/SiO_x/Co/CoOOH photoanode under 100 mW cm⁻² AM 1.5 irradiation (red). c,d, ln(J)-V plots collected by measuring the limiting photocurrent and photovoltage of photoanodes at different light intensities for the photoanode with 10 mC cm⁻² (c) and 200 mC cm⁻² (d) cobalt. e, Measured (o) and simulated (solid line) photoresponse of the photoanode under 100 mW cm⁻² (red) and 200 mW cm⁻² (blue) AM 1.5 irradiation in 1 M KOH using Eq. 1 and values of J_s and n measured in (c) for the photoanode with 10 mC cm⁻² photoanode in a 1 M KOH electrolyte with a series of potassium hexacyanoferrate(III) concentrations under 100 mW cm⁻² AM 1.5 irradiation. The open-circuit photovoltage is independent of the solution potential. (From reference 4).



Figure 2 | **Solid-state characterization of the electrodeposited n-Si/SiO_x/Co junction. a,** Current-voltage response of n-Si/SiO_x/Co solid-state cell with an In front contact at a 10 mV s⁻¹ scan rate showing diode behavior. Inset shows schematic of the solid-state cell. **b,c** Solid-state Mott-Schottky plots collected at reverse bias with a frequency of 100 kHz and scan rate of 10 mV s⁻¹ showing barrier heights (ϕ_{bh}) of 0.90 eV (**b**) and 0.74 eV (**c**) for n-Si coated with 10 mC cm⁻² (**b**) and 200 mC cm⁻² (**c**). **d**, Flat band potentials of solid state cells as a function of cobalt

coverage determined by Mott-Schottky plots collected at a 10 mV s⁻¹ scan rate and 100 kHz frequency. The flat band potential increases as the Co layer thickness decreases. At the lower Co coverages the Co has not coalesced into a dense film. (From reference 4).



Figure 3 Schematic of solid-state Schottky barrier and electrodeposited n-Si/SiO_x/Co/CoOOH junctions. a, Solid-state, epitaxial n-Si/CoSi₂ Schottky barrier produced in vacuum with 0.61 eV barrier height (ϕ_{bh}). b, Electrodeposited n-Si/SiO_x/Co/CoOOH junction of thick Co layer (200 mC cm⁻²) with barrier height of 0.74 eV. c, Electrodeposited n-Si/SiO_x/Co/CoOOH junction of thin, inhomogeneous Co layer (10 mC cm⁻²) with barrier height of 0.91 eV. The photogenerated holes are collected at the Co/CoOOH islands where they oxidize water to oxygen gas. (From reference 4).

Electrodeposition of Epitaxial Perovskite Thin Films:

An electrochemical/chemical route is introduced to deposit both textured and epitaxial films of methylammonium lead iodide (MAPbI₃) perovskites. The perovskite films are produced by chemical conversion of lead dioxide films that have been electrodeposited as either textured or epitaxial films onto [111]-textured Au and [100] and [111] single-crystal Au substrates. The epitaxial relationships for the MAPbI₃ films are MAPbI₃(001)[010]||PbO₂(100)<001> and MAPbI₃(110)[111]||PbO₂(100)<001> regardless of the Au substrate orientation, because the in-plane order of the converted film is controlled by the epitaxial PbO₂ precursor film. The textured and epitaxial MAPbI₃ films both have lower trap densities and higher photoluminescence intensities than polycrystalline films produced by spin coating.



Figure 4 XRD patterns of as-deposited PbO₂ (black), MAPbI₃ film converted at 75 °C (red) and at -10 °C (blue) deposited on Au(100) (a), and Au(111) (b) substrates. (c) (111) pole of electrodeposited PbO₂ on Au(100). (d) (111) pole of electrodeposited PbO₂ on Au(100). (d) (111) pole of electrodeposited PbO₂ on Au(100). (f) (224) pole of MAPbI₃ film converted at 75 °C on Au(100). (f) (224) pole of MAPbI₃ film converted at 75 °C on Au(100). (f) (224) pole of MAPbI₃ film converted at 75 °C on Au(100). (f) (224) pole of MAPbI₃ film converted at 75 °C on Au(100). (f) (224) pole of MAPbI₃ film converted at 75 °C on Au(100). (f) (224) pole of MAPbI₃ film converted at 75 °C on Au(111). (g) Interface model of MAPbI₃(001) (blue) on PbO₂(200) (red). (h) Interface model of MAPbI₃(110) (blue) on PbO₂(200) (red). (i) Interface model of MAPbI₃(110) (blue) on MAPbI₃(001) (orange) showing a lattice mismatch of only 0.51%. The inset in (i) is an SEM image showing the intergrowth of two [110]- and [001]-oriented MAPbI₃ crystals obtained at 50 °C. (Unpublished).



Figure 5 Plan-view SEM images of as-deposited PbO_2 (a,d), MAPbI₃ films converted at -10 °C (b,e) and at 75 °C (c,f) on Au(100) and Au(111) substrates. (Unpublished).



Figure 6 (a) Absorption (blue squares) and photoluminescence (PL) spectra (right circles), measured for the [110]-textured MAPbI₃ film converted at 75 °C on a gold-coated glass substrate. (b) Comparison of PL spectra of the epitaxial (green squares) and [110]-textured (red circles) MAPbI₃ films converted from PbO₂ at 75 °C and polycrystalline film converted at room temperature from spin-coated PbI₂ (blue triangles). The PL intensity was normalized to the material volume. (c) Trap density measurements for the epitaxial MAPbI₃ film converted from PbO₂ at 75 °C on Au(100) (green circles), a [110]-textured film converted from PbO₂ at 75 °C on Au-coated glass (red triangles) substrates, and the polycrystalline film converted at the room temperature from spin coated PbI₂ on Au-coated glass substrate (blue squares). (Unpublished).

Future Plans

1. Study the interfacial energetics of other nanocrystalline, inhomogeneous catalyst contacts to semiconductors.

2. Explore the use of a nanometer-thick Au epitaxial layer on Si(111) as an inexpensive proxy for bulk Au single crystals, as a protecting layer for photoelectrodes, and as a way to integrate electrodeposited epitaxial structures with traditional Si devices.

2. Produce a working cell based on the epitaxial perovskites.

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Enhanced Materials Based on Submonolayer Type-II Quantum Dots

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Program Scope

During the past several years we have investigated a class of nanostructured materials that we refer to as submonolayer (SML) type-II quantum dots (QDs) made from wide bandgap II-VI semiconductors. Our goal is to understand and exploit their tunable optical and electrical properties, by taking advantage of the type-II band alignment and quantum confinement effects.¹ Type-II ZnTe QDs in a ZnSe host are particularly interesting because of their relatively large valence band and conduction band offsets. Exploring the potential for designing new materials with enhanced properties was the primary motivation of our previous award. During that time we advanced our understanding of these novel nanostructures and our ability to control and manipulate their structural properties and we obtained materials with new and enhanced properties. We also developed experimental approaches to characterize the structures with high precision and insight. We have also shown that a variation of this material system, ZnTeSe QDs in a ZnCdSe host material, has nearly ideal properties for the fabrication of intermediate band solar cells (IBSC), ^{2,3} a novel high performance photovoltaic device that has yet to be realized with real materials.

Over the last two years we have greatly advanced our understanding of these materials and their growth habits. We have developed a methodology to correlate the dot size and density with growth parameters. We have developed a new approach for the structural characterization of these materials using high resolution X-ray diffraction (HR-XRD), from which the size and distribution as well as the shape of the dots can be extracted, and we have investigated the effects of this shape anisotropy on the optical and magneto-optical properties of the dots. It should be noted that previous modeling efforts have used quantum well based analysis. This is the first direct account of quantum dot shape and distribution in the analysis of XRD from multilayer QDs. Finally, we have continued to make progress in demonstration of the IBSC made from these materials.

Recent Progress and New Results:

1. Measurement and control of size and density of type-II ZnTe/ZnSe submonolayer quantum dots grown by migration enhanced epitaxy

Combining a variety of characterization tools, including XRD and SIMS to establish the Te content and the structural parameters, and photoluminescence (PL) and magneto-PL to estimate the QD thickness, QD radial sizes and weighted QD volume, the dependence of the QD size (thickness and radius) as well as the QD areal density on the Te content in the samples were extracted.

First, to examine the effect of varying growth conditions on the formation of the type-II QD structures, a new parameter ' τ ' (the product of the Te flux times the number of MEE cycles used during growth) was introduced, as a measure of actual Te content in the samples. The optical characterization was done by performing PL as well as magneto-PL experiments at 10 K.

As previously reported, 'green band' (<2.7 eV) originates from the QD.⁴ This part of spectra were fitted with Gaussian lineshapes, and the corresponding peak positions were used to estimate the average QD size, specifically the thickness, by solving the 1-D Schrödinger equation. Magneto-PL was used to obtain an accurate estimation of the radial sizes of these SML QDs, through the observation of excitonic Aharanov-Bohm (AB) effect.^{5, 6} The average QD radii for the samples in this study are estimated to be about 13 to 20 nm, justifying the claim that most of the confinement in these disc-shaped QDs is along the growth direction i.e. due to the QD thicknesses. The combined result of the calculated QD thicknesses and radii overlaid on the complete PL spectrum for the set of samples investigated is shown in Fig. 1.



Figure 1. Combined diagram of the spectral dependence of QD radii and thicknesses overlaid on the corresponding PL spectra. The green bands are specifically highlighted as they correspond to QD-related emissions.

Upon obtaining the spectral distribution of QD radii and thicknesses, the intensities of the green bands were used to estimate weighted OD volume over the full PL spectrum for each of the samples, and with this, the density of QDs was then estimated from the calculated QD volume. We then plot the average QD radii and thicknesses as well as areal QD density vs. the corresponding values of τ for a set of samples A through F in Figs. 2 (a) and (b).



Figure 2. (a) Plot showing average QD radii and thicknesses as a function of τ . (b) Plot showing the dependence of areal QD density on τ ; dashed lines are for eye guidance only.

Two important conclusions were reached from this study. First, we noted that concentrations at least one order of magnitude higher would be required to form a full ZnTe-rich monolayer (i.e. for the QDs to physically coalesce into a continuous layer). Secondly, the
observed dependence of average QD size and density as a function of Te flux as well as number of Te MEE cycles shows that these are the key parameters to control QD dimensions and distribution.

2. Determination of shape anisotropy in embedded low contrast submonolayer quantum dot structures:

We have developed and implemented a powerful characterization formalism which utilizes experimental and simulated high resolution in-plane reciprocal space maps (RSM) to investigate the morphology of embedded type-II ZnTe/ZnSe SML QDs with required precision and detail. Our results clearly demonstrate that this combination of characterization techniques is uniquely suited to elucidate the morphology of these hard-to-image SML QD structures. Our approach provides a fast, accurate and precise way of characterizing embedded ultra-small QD arrays.

The QD morphology was deduced from diffuse scattering data obtained by measuring inplane RSM. Specific trajectories in reciprocal space have been recorded to measure the in-plane map around the (004) SL(-1) peak. A set of rocking curves along 360° has been merged to obtain proper $q_x - q_y$ map as shown in Fig. 3(a). The width Δq_x shows periodic oscillations as a function of azimuthal angle ϕ ; hence in-plane RSM presents a strong anisotropy in the diffuse scattering signal.



Figure 3. (a) In-plane reciprocal space map around satellite SL(-1) of (004) Bragg peak (inset) depicting clear anisotropic shape. (b) Simulated rocking curves as a function of azimuthal angle for a known size dispersion of elongated QDs.

To explain the experimental observation, in-plane diffuse scattering has been computed using kinematic sum and *realistic* QD shape and size distribution, with the aid of magneto-PL derived QD size dispersion estimates (Fig. 3 (b), inset). A set of different QD configurations has been computed to reproduce the experimental results (Fig. 4). It was observed that QD size distribution presenting centro-symmetric shapes leads to centro-symmetric diffuse scattering pattern, and that ellipsoid dots with random orientation leads also to a similar centro-symmetric feature. Only an assembly of elongated ellipsoidal QDs with definite orientation explains the experimental signal. Thus, ellipsoidal QDs elongated along [110] axis with varied in-plane aspect ratios (i.e. b/a, as



Figure 4. (a) - (c) Simulated RSMs of QDs with various shapes and orientations, the insets show the corresponding QD configuration. (d) Schematic of the disc-shaped embedded SML QDs elongated along [110] orientation.

shown in Fig. 4.) were used for the purpose of the simulations. The simulations, as shown in Fig. 3(b), present clear evidence of the anisotropically shaped QDs elongated along [110] orientation. The best match with the experimental data was obtained for the QD aspect ratio of 1.17.

Anisotropically shaped SK grown QDs have been reported to show optical anisotropy as observed in their PL emission.^{7,8} In order to study the effect of the asymmetric shape of these ultra-small QDs, we investigated the linear polarization of the PL at 8 K. The contour map showing PL spectra as a function of the angle between axis of the linear polarizer and the [110] axis of the sample is shown in Fig. 5(a). Moreover, the axis of polarization and the asymmetric shape of the $\omega - \varphi$ scan show excellent correlation (Fig. 5(b)) further confirming the presence of



Figure 5. (a) Linearly polarized photoluminescence spectra plotted as a function of azimuthal angle revealing in-plane anisotropy; (b) correlation between the width of rocking curve and the intensity of linearly polarized PL emission as a function of azimuthal angle ϕ .

considerations is 1.27 for the sample studied by XRD.

Future Plans:

We have begun to investigate other materials, namely CdSe/CdTe heterostructures and QDs, to identify other systems in which similar phenomena may be observed. We are also pursuing doping of the ZnTe/ZnCdSe QD structures for demonstration of IBSC behavior.

the elongated QDs, preferentially orientated along [110] direction.

We also performed numerical calculations of the optical anisotropy based on the difference in occupation of p_x and orbitals chosen to p_{v} align the [110] and $[1\bar{1}0]$ axes. respectively.^{8,9} We found that the aspect ratio derived from these

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- S. Dhomkar, H. Ji, R. Wu, Z. Lu, J. Ludwig, D. Smirnov, M. C. Tamargo, and I. L. Kuskovsky Magneto-photoluminescence of Tellurium Isoelectronic Bound Excitons in Zn-Se-Te in the Presence of Type-II Submonolayer Quantum Dots.

The Dynamics of Complex Two-Phase Mixtures During Coarsening: From Dendritic to Bicontinuous Mixtures

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Program Scope

Dendrites frequently form during solidification into an undercooled melt. In systems with nearly isotropic interfacial energy, these dendrites possess secondary and sometimes even tertiary arms. In systems with anisotropic interfacial energy, the growth shapes can be highly crystallographic and thus of very different morphology from those in systems with isotropic interfacial energy. The resulting two-phase mixtures are topologically and morphologically complex with spatially varying mean and Gaussian curvatures. These solid-liquid mixtures are one example from a large class of morphologically and topologically complex structures found in nature that undergo coarsening. Included in this class are the bicontinuous two-phase mixtures produced following spinodal decomposition and ordering in crystals. Understanding the coarsening process in all of these systems requires theory, simulation, and experiments that capture their three-dimensional topology and morphology. Given the complicated morphology and topology of these systems it is not surprising that our understanding of this process is in its infancy.

Recent Progress

Shown in Figure 1(a) and (c), are results from coarsening of Si particles in an Al-Si eutectic liquid. These data were obtained using 4D phase contrast tomography. Phase contrast tomography is employed because of the small atomic number difference between Si and Al. There is a striking change in the morphology of the particles during coarsening from those with slow-moving and low-interfacial-energy {111} interfaces to a much more isotropic structure. The degree of isotropy is quantified by measurements of the probability of finding a patch of interface with a given shape factor S and curvature C(1). Using this representation, interfacial patches that are solid cylinders have S = 0.5, liquid cylinders S = -0.5, solid spheres S = 1.0liquid spheres S = -1.0 and saddle shaped surfaces have -0.5 < S < 0.5. The curvature C is zero for flat interfaces, and nonzero for interfaces with any curvature. In Fig. 1 the curvature is normalized by the surface area per volume, S_{ν} . Here the interface shape distribution is the probability of finding a patch of interface with a given C and S. In the early stage of coarsening, a significant fraction of the interfacial area is nearly flat, which is evident by the large, broad peak with C/ $S_v < 0.5$. There is a strong peak at S = 0.5 that has a large range of curvatures up to nearly 4. These large curvatures are the patches that make up the edges of the plates. By contrast, at later time most of the flat interfaces and patches on edges of the plates with large C have disappeared. The surprising result is that, as the coarsening process proceeds, the particles are

not evolving towards the Wulff shape, which is the equilibrium shape based on the interfacial energy and is a shape consisting of {111} and/or {100} facets for this system. Electron Backscatter Diffraction (EBSD) analysis shows that certain Si plates are defective with twin boundaries running parallel to the {111} solid-liquid interfaces. These twins can provide sources of the steps at the solid-liquid interfaces that allow the interfaces to grow and dissolve in a non-crystallographic fashion. The high density of twins within the structure leads to the development of a nearly morphologically isotropic structure during coarsening. This illustrates the qualitatively different evolution process in systems with anisotropic interfacial energy and mobility compared with two-phase mixtures with nearly isotropic interfacial energy and constant mobility.



(A) Microstructure after 10 min. of coarsening, (B) Interface shape distribution corresponding to the microstructure in (A), (C) Microstructure after 60 min. of coarsening (D) Interface shape distribution of the microstructure in (C).

The mathematical description of the evolution of the mean and Gaussian curvatures, which together define the interfacial morphology, can be derived from differential geometry for a given interfacial normal velocity (2). Due to their relative simplicity, as compared to structures that involve multiple feature sizes (such as dendritic structures), we have chosen to examine the implication of these questions for the bicontinuous structures that form from phase decomposition (in the case of conserved dynamics) or ordering (in the case of nonconserved dynamics). In spite of their relative simplicity, a theoretical study of the dynamics of coarsening is still challenging because bicontinuous structures inherently possess multiple length scales, as the interfaces

have two independent curvatures. Thus, we must develop a framework for theoretical development. To this end, we considered two cases: (1) interfacial evolution due to nonlocal bulk diffusion and (2) interfacial evolution due solely to the interfacial curvature.



evolved with Allen-Cahn dynamics, colored with the time derivative of mean curvature. The spatial variation in DH/Dt is much larger than the mean curvature (or local velocity).

We first focused on the evolution of interfacial curvature by examining the evolution of the Allen-Cahn structure (3). Under the Allen-Cahn dynamics, the interfacial velocity is directly proportional to the mean curvature (i.e., the structure evolves by "motion by mean curvature"), and therefore it provides an ideal test bed with which to investigate the evolution of a bicontinuous structure. The results show that the evolution proceeds with some interfaces evolving toward topological singularities (pinching) while the majority of interfaces flatten. Most notably, we find that, while the normal velocity is solely a function of the mean curvature H, its evolution as quantified by DH/Dt is not simple at all, as shown in Fig. 2. We find that the terms involving the second derivatives of the velocity are very important. Consequently, the evolution of *H* at a point depends on the values of *H* in its neighborhood and, despite the local

nature of the motion-by-mean-curvature equation for the normal velocity, the evolution of H is nonlocal. What are the implications of these findings to conserved systems, the systems in which we are ultimately interested? To answer this question, we began performing preliminary simulations with Cahn-Hilliard structures. In particular, we have studied cases where diffusivities are equal between the two phases, as well as cases where diffusivities are not equal (as in solid-liquid mixtures).

Future Plans

Building upon these results, we plan to examine, both theoretically and experimentally, the distribution of interfacial velocities for a given pair of principal interfacial curvatures, the effects of a difference in diffusion coefficients on the morphology of solid-liquid mixtures during coarsening, the role of the Gaussian curvature in setting the interfacial velocities, and the coarsening process in systems with highly anisotropic interfacial energy such as that of Al-Si. The goal is to produce a theory for coarsening of these complex structures.

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Synthesis of Three-Dimensional Nanowire Architecture with Enhanced Performance in Solar Energy Harvesting

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Program Scope

The objective of this project is to obtain in-depth understanding of the nanoscale crystal growth behavior in a surface-reaction-limited pulsed chemical vapor deposition (SPCVD) process, and thereby achieve well-controlled syntheses of three-dimensional (3D) nanowire (NW) arrays inside highly-confined spaces. An experiment-based project is proposed to study the nucleation and anisotropic crystal growth mechanisms of titanium dioxide (TiO₂). This understanding will then be applied to controlling the composition and dimensionality of TiO₂ NWs and eventually to the growth of other functional materials. The outcome of this project will be a powerful NW synthesis technique that can uniformly grow NW arrays of controlled composition and morphology inside 3D-confined and submicron-sized spaces, thus enabling the creation of a variety of new functional nanomaterial architectures.

Recent Progress

SPCVD technique has been developed in our lab to create high-density uniform 3D branched NW architectures, which offers favorable surface area and charge transport properties for developing high performance photoelectrodes.^[1] By performing atomic-scale elemental analysis and high resolution scanning transmission electron microscopy (HR-STEM) study on the surface of a Si NW coated with a 10-cycle TiO₂ by 600 °C SPCVD, we discovered that the high-temperature SPCVD of TiO₂ nucleation followed the Ostwald-Lussac (OL) Law and the 1D TiO₂ anisotropic crystal growth was governed by the oriented attachment (OA) mechanism.^[2]

Following this research, we applied SPCVD of TiO₂ NRs to ZnO NW backbones.^[3] By introducing TiCl₄ vapor pulses to ZnO NW templates, we obtained TiO₂ nanotubes with well-preserved dimensions and morphology. This process involved the cation exchange reaction between TiCl₄ vapor and ZnO solid and the diffusion of reactants and products in their vapor or solid phases, which was found to be a manifestation of the Kirkendall effect.

We discovered that 2 cycles of TiO_2 SPCVD on ZnO NWs roughened the NW's surface (Fig. 1a). To understand this process, EELS mapping was conducted. Ti distribution clearly matched the grain morphology along the polycrystalline shell. The Zn map revealed a universal distribution of Zn in the entire structure with strong Zn signals located at the center region representing the remaining ZnO core. The homogeneous Zn distribution along the entire shell region suggests that the Zn elements from the core were diffused into and traveling through the TiO₂ shells during the growth. When only TiCl₄ vapor was present, 10-cycle deposition also

completely removed the ZnO core and same anatase TiO₂ polycrystalline nanotubes were obtained (Fig. 1b). When H_2O vapor precursor was used exclusively, only small pores were created on the ZnO NW surface. This comparison reveals that H₂O was insignificant an component in the ZnO TiO_2 conversion, to and the O in TiO₂ can be completely



Figure 1 a, STEM image and EELS spectrum imaging of the Ti, Zn, and O elements on a 2-cycle sample. **b,** A TiO₂ nanotube formed via 10 cycles of TiCl₄ pulse. **c,** Amorphous TiO₂ coated ZnO NW after 10 hours annealing. **d,** Schematic illustration of the Kirkendall effect in TiO₂ nanotube evolution. **e,** Cross-sectional SEM image of a 3D TiO₂ nanoforest formed on ZnO NW templates. Inset is a TEM image of an individual branched TiO₂ NW. **f,** Enhanced PEC performance of 3D TiO₂ nanoforest.

provided by ZnO following the cation exchange reaction. The ZnCl₂ by-products would most likely exist in its vapor phase, which was favorable for rapid diffusion and complete removal of the Zn species from the core. We also found that simply annealing amorphous TiO₂-coated ZnO only formed a core-shell structure with yielded multiple voids were observed at the core/shell interface (Fig. 1c). This experiment revealed that solid-state diffusion of ZnO species cannot explain the vanishing of ZnO in the heterostructure and formation of pure TiO₂ phase.

Figure 1d schematically shows the Kirkendall effect in responsible for the formation of hollow TiO_2 nanostructures. When $TiCl_4$ vapor is first introduced, the exterior surface of the ZnO NW quickly converts to TiO_2 and generates $ZnCl_2$ by-product. Meanwhile, initial voids were created at the defective core/shell interface. Once the surface is fully covered by the TiO_2 shell, further removal of ZnO required the ZnCl₂ species to diffuse outward. The cation exchange reaction between $TiCl_4$ and ZnO occurs at the TiO_2/ZnO interface and TiO_2 outer surface, resulting inward and outward growth of the shell, respectively. Upon the consumption of ZnO at the TiO_2/ZnO interface, the void size increases leaving a typical Kirkendall bridge morphology. Eventually, the entire ZnO core is consumed yielding a hollow TiO_2 nanotube.

The TiO₂ nanotube arrays could serve as an excellent scaffold to support dense TiO₂ NR branch growth *via* our SPCVD technique, yielding a pure TiO₂-phased 3D NW architecture (Fig. 1e). TEM characterization on a single hierarchical NW structure revealed the dense singlecrystalline TiO₂ NR coverage and the polycrystalline hollow trunk (Inset of Fig. 1e). PEC water splitting experiments were conducted to explore the application potential of the 3D TiO₂ nanoforest in comparison to TiO₂ film-coated ZnO NWs. Figure 1f shows the photocurrent density (J_{sc}) versus applied bias acquired from the 3D TiO₂ nanoforest and the two reference samples under the illumination of a 150 W Xe lamp. The three samples exhibited similar open circuit voltage (V_{oc}) and followed the same trend; whereas, their J_{SC} were dramatically different. Owing to the enlarged surface area, the 3D TiO₂ nanoforest achieved a J_{SC} of ~3.14 mA/cm², which was remarkably higher than other reported TiO₂ NW-based PEC electrodes. This discovery offers a



new route for hierarchical functional nanomaterial assembly and application.

Likewise, the 3D TiO₂ NW architecture is a superior electrode design for photovoltaic (PV) devices compared to NWs or nanoparticle systems in terms of improved large surface area and charge transport properties. CH₃NH₃PbI₃ perovskite solar cells were fabricated based on such 3D TiO₂ NW architectures with a length variation from ~600 nm to ~1.4 μ m (Fig. 2a).^[4] By increasing the length of the 3D TiO₂ scaffolds, J_{sc} was increased accordingly, while V_{oc} , fill factor (FF) of cells were decreased. The enlarged J_{sc} is attributed to the enhanced hole injection efficiency and increased light absorption from longer TiO₂ nanostructures. The length-related reduction of V_{oc} and FF is believed to be a result of decreased charge generation efficiency, increased charge recombination and higher electron transport resistance. The best PCE was offered by the ~600 nm 3D TiO₂ scaffold with a value of 9.0%, which was 1.5 times higher than 1D TiO₂ nanostructures made through the same process. The high-density 3D TiO₂ architecture

on ZnO NW template.



Figure 3 (a) SEM and (b) TEM of SPCVD V_2O_5 NRs on ZnO NWs. (c) HRTEM of the NW backbone showing polycrystalline V_2O_5 lattices. (d, e) HRTEM images of a V_2O_5 NR.

allowed higher perovskite loading and enhanced light harvesting compared with simple 1D nanostructure arrays. In addition, PV cells comprising 3D TiO₂ are found to be favorable in suppressing the hysteresis effect that is often observed from planar perovskite SCs (Fig. 2b). The 3D hierarchical NWs morphology offers a promising candidate for understanding the property-performance relationship in perovskite solar cells and developing high performance solar energy harvesting devices.

Through SPCVD, VO_x NRs were also synthesized on ZnO NW cores using

VOCl₃ and H₂O as the precursors.^[5] Dense VO_x NRs uniformly distributed on the ZnO NW templates (Fig. 3a). The VOx NRs exhibited a necklace-like morphology (Fig. 3b) and the surface was covered with an amorphous layer (Fig. 3d,e). In addition, no ZnO phase was found from the polycrystalline backbone of hierarchical structure (Fig. 3c). These observations are consistent with the vapor-phase OA and Kirkendall effect in SPCVD process, suggesting our understandings on SPCVD mechanisms and kinetics could be generally applied to different material systems. This development demonstrated the versatility of the SPCVD technique in creating 3D NR branches from different material systems.

Future Plans

This is toward the end of our current DOE award. The understandings obtained through this award opened many new opportunities in designing 3D NW architectures with improved properties or new functionalities. Our future research plan is to follow these research achievements, and address three further key aspects of SPCVD. (1) Study the operation of the OL law of TiO₂ phase transition on heterogeneous, homogeneous, and carbon surfaces, and thus understand and eventually control the nucleation of TiO₂ NRs on desired material surfaces to create multilevel branching architectures and carbon-based heterostructures. (2) Understand the diffusion and aggregation kinetics of crystallites embedded in amorphous layers and reveal how the amorphous layer controls the OA process. (3) Understand the kinetics of ionic diffusion and surface etching reaction operated by the Kirkendall effect during SPCVD, and thereby achieve rational control of the morphology and phase of TiO₂ and perovsites NR branches.

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Boron-based nanostructures, stability, functionality and synthetic routes

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Program Scope

We focus on theoretical and computational modeling line of work, with general direction towards investigation of boron (B) clusters-fullerenes and of planar 2D (two dimensional) Bbased materials. Specific sub-tasks, chosen based on priority or continuity criteria, include the following. We perform a theoretical assessment of the stability and the ways of confinement of the recently discovered pure boron buckyballs [1], as a spectacular confirmation of our early predictions [2, 3]. We explore the ways of (conceptual) unfolding of the B₄₀ cluster, to see if this can lead to unanticipated novel planar material. We further undertake a theory-guided approach to 2D-materials synthesis, to assist experimentalists with not only "final target" but also the ways to possibly reach this target. We expand this novel direction, already demonstrated on pure-B layers towards other important example, including h-BN.

2D pure boron is polymorphic, and we will verify the shape of the formation energy hull with higher precision (which take larger cell to be considered in the CE (cluster expansion [4]) calculations. This is important not to miss, due to technicality, any of real sharp preferred forms. Important physics aspect that must be explored is the possibility of very high thermal conductivity of B-sheets and also hypothetical possibility of superconductivity of these metallic phases with potentially large electron-phonon coupling. Within pure-boron 2D family, we investigate 2D cluster-assembled B12-boron sheets, as a legitimate alternative to the monoatomic layers.

Monolayer h-BN is isomorphic to graphene and its alloying with C can yield ver useful band gap tenability, as demonstrated in our recent collaboration with Jilin University, China (Zhang et al. *Nanoscale*, 2015).

Recent Progress

Density functional theory is accepted as an accurate way to determine the ground electronic state of a material and its stable structure, not necessarily the most stable. Augmenting it by further search-algorithms like cluster expansion and more recently, grid-free evolutionary methods, makes it possible to find unknown materials structures as global minima. Moreover, if the search is



Predicted (left, our published work) versus STMobserved + simulated (right) monolayer B on Ag(111) [5].

performed in presence of a templating or even catalytic substrate, this further enables predicting the conditions and likely synthetic routes. Boron layers highlight the success of these developments, as detailed below.

While the experimental realization of 2D boron sheets remains a challenge, it is important to theoretically investigate the possible fabrication methods. Recently we have explored the formation of B sheets on metal (Cu, Ag, Au) and metal boride (MgB2, TiB2) substrates via first-principles calculations. Our results suggest that B sheets can be grown on the Ag(111) or Au(111) surfaces by deposition. B atoms decomposed from precursor, and driven by the gradient of chemical potential, will assemble into 2D clusters and further grow to a larger sheet, while formation of three-dimensional B structures is impeded due to high nucleation barrier (Liu et al. *Angew. Chemie*, 2013).

Further, after revealing the polymorphisms of 2D B, we find how this can be altered in presence of substrates. Indeed, typical two-dimensional (2D) materials—such as graphene and boron nitride—have specific lattice structure independent of external conditions. In contrast, the structure of 2D boron sensitively depends on metal substrate, as we have shown (Zhang et al. *Angew. Chemie*, 2015) using cluster expansion method and a newly developed surface structure-search method, both based on first-principles calculations. The preferred 2D boron on weaker interacting Au is nonplanar with significant buckling and numerous polymorphs as in vacuum, whereas on more reactive Ag, Cu and Ni, the polymorphic energy degeneracy is lifted and a particular planar structure is found to be most stable. We further show that a layer composed of icosahedral B_{12} is unfavorable on Cu and Ni but unexpectedly becomes a possible minimum on Au and Ag. The substrate-dependent 2D boron choices originate from a competition between the strain energy of buckling and chemical energy of electronic hybridization between boron and metal. As a result we have not only identified Ag(111) as promising substrate but also which specific 2D B configuration should form (Zhang et al. *Angew. Chemie*, 2015). Recent experimental evidence [5] appears to be in remarkable accord with this prediction.

Future Plans

Future plans include to move forward from theoretical determination of possible 2D B structures to more detailed analysis of their properties: stability (cautiously) with possibly necessary confinement, thermal transport, and especially superconductivity assessment. The latter includes detailed band structure and Fermi surface analysis, electron-phonon interaction and estimated of the T_c values [6].

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Mapping the synthetic routes for 2-dimensional materials

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Program Scope

This project is motivated by three concurrent factors: (i) an intensified worldwide interest and research in two-dimensional materials, which emphasized the need for a deeper understanding and control of their synthesis; (ii) success in our laboratory in developing a general approach to modeling the growth of graphene, with basic ideas transferable to the broader 2D-materials family; (iii) emergent findings-including some in our own work-of specific functionalities among 2D materials, relevant to DOE interests, such as potential battery electrodes [1], catalytic activity, tunable energy band gaps for electronics, interfaces in heterogeneous systems for photovoltaics, etc. These very factors (i-iii) make the effort timely, as the rapid development of basic science of 2D materials synthesis facilitates their availability, improve quality, and diversify keenly sought functionalities for important practical applications. Indeed, the discovery of novel physics in graphene, combined with the hurdle of "opening" its electronic gap, has ignited the interest and expanded the scope of research worldwide, to the extended family of 2D-materials "beyond graphene". This raised a number of broader compelling questions about the ways of making such monoatomic layers. The exfoliation from natural bulk precursors (3D bulk to 2D layer) is not scalable. On the other hand, their synthesisoften called "growth" due to visible change in size and shape-through chemical vapor deposition (CVD) involves complex gas-solid chemistry, which often works empirically, but its theoretical understanding and sentient design remain in infancy. This is the direction in which we embark to explore: developing state of the art multiscale models of 2D-layers on substrates and of atomistic mechanisms of their nucleation (when the 2D island may or may not be preferred over the 3D cluster) and subsequent growth. Our unique combination of methods, from the first principles density functional theory (for underlying forces and interface dynamics) to the nucleation and growth theories, organized together in the nanoreactor mass-flow diagram [2], is being connected to phenomenological larger-scale models (Monte Carlo simulations, phase field, level sets). This enables predicting the growth rates and morphology evolution on different substrates and at different conditions. We explore how a sentient choice of a substrate, interacting at just the right level with the commencing nucleus, can facilitate growth of planar materials forms, even for compositions currently unavailable. Our project materials focus is at two levels. The primary set includes those of already established great interest: graphene (C), planar hexagonal boron nitrogen (h-BN, "white graphene"), and transition metal disulfides like MoS2. However, we also investigate nucleation and growth of emergent or even hypothetical 2D materials: phosphorene (P), stanene (Sn), silicene (Si), borene (B), and possibly others. Success of this project, even if limited to a subset of material examples, could be enormous, by leading to efficient synthesis and availability of materials with novel desired properties. It should impact

fundamental studies in this field, as well as permit various applications in devices, energy utility and production, of commercial and defense significance.

Recent Progress

One line of research was in exploring role of defects emerging in the course of synthesis or other fabrication (e. g. exfoliation, remaining almost exclusive way in case of phosphorene). The deep gap states created by defects in semiconductors typically deteriorate the performance of (opto-) electronic devices. This has limited the applications of two-dimensional (2D) metal dichalcogenides (MX₂), and underscored the need for a new 2D semiconductor without defect-induced deep gap states. In this work [Liu et al. *Nano Lett.* 2014, Wang et al. *Nanoscale* 2015] we demonstrate that a 2D mono-elemental semiconductor is a promising candidate. This is exemplified by first-principles study of 2D phosphorus (P) a.k.a. phosphorene, a recently fabricated high-mobility semiconductor. Most of the defects, including intrinsic point defects and grain boundaries, are electronically inactive, thanks to the homo-elemental bonding, which is not preferred in hetero-elemental system such as MX₂. Unlike MX₂, the edges of which create deep gap states and cannot be eliminated by passivation, the edge states of 2D P can be removed from the band gap by hydrogen termination. We further find that both the type and the concentration of charge carriers in 2D P can be tuned by doping with foreign atoms. Our work sheds light on the role of defects in the electronic structure of materials.

Another important line of progress is shaping as we study how graphene (and more generally 2D-material) morphology is affected by lower-symmetry metal surfaces supporting it during synthesis. For the Ni(111) triangular surface we find different ground-state structures (hexagonal and Klein) of zigzag edges in different directions and predict from first principles the equilibrium and growth shapes of graphene islands to explain the diversity of experimentally observed shapes. Then we



Observed and MC simulated variety of shapes of graphene on Ni(111) [Artyukhov et al.PRL 2015]

present experimental observations of shapes of graphene islands grown simultaneously on different crystallographic surfaces of Cu, and explain the origin of these shapes in the symmetry of respective Cu surfaces—(111), (110), (100)—using Monte Carlo simulations of growth. The insight straightforwardly generalizes to other substrates and 2D materials. We note that for equilibrium shape, edge energy variations δE manifest in just slightly distorted hexagons with different ground-state edge structures. In growth or nucleation, energy variation enters exponentially as $\sim e^{\delta E/kBT}$, strongly amplifying the symmetry breaking, up to completely changing the shapes to triangular, ribbonlike, or rhombic (see Figure).

Future Plans

Future plans include the completion of extensive work, including the code development, on the phase field and multi-phase field modeling of 2-dimensional growth and especially fusion of multi-nuclei in determining the shapes of growing crystal. This already allows us to explain a number of puzzling shapes in numerous reported microscopy data (among them, notably, so called bowties and David Stars), which includes explanation of dominating inversion twins and grain boundaries [3]. Another line of work is to expand the application of nanoreactor approach [2] to growth model of h-BN, with borazine or ammonia borane as precursors.

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Atomic Layer Deposition (ALD) of Metal and Metal Oxide Films: A Surface Science Study

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i) Program Scope

The general objective of our project is to develop a molecular-level understanding of the thermal reactions that organometallic compounds used for atomic layer deposition (ALD) follow on surfaces. ALD is poised to become one of the dominant technologies for the growth of nanometer-sized conformal films in many industrial applications. In microelectronics in particular, the growth of diffusion, adhesion, and protection barriers and of metal interconnects is central to the buildup of diodes, transistors, and other elements within integrated circuits. All these processes require the deposition of isotropic films on complex topographies under mild conditions and with monolayer control. ALD is particularly suited to satisfy all those conditions, but many questions concerning the underlying surface chemistry need to be answer before it can find widespread use.

Our mechanistic studies of the ALD-related reactions is being pursued with the aid of a number of surface-sensitive techniques, including X-ray photoelectron (XPS), temperature programmed desorption (TPD), and infrared (IR) spectroscopies. One present focus is the study of processes for the deposition of copper metal interconnects and of diffusion barriers for those, a central need in the microelectronics industry. Specific questions are being addressed in terms of the kinetics and mechanisms of the reactions involved, and also in connection with the composition and morphology of the resulting films. This knowledge will be directed to the design of ALD processes that operate under the mildest conditions possible and deposit stoichiometric and pure films with good density, low resistance, and smooth surfaces.

ii) **Recent Progress**

In the initial stages of this project, we have characterized the thermal chemistry of copper(I)-N,N'-di-*sec*-butylacetamidinate on Ni(110) single-crystal and cobalt polycrystalline surfaces under ultrahigh vacuum (UHV) conditions by XPS and TPD [1; 2]. This chemistry was later tested on a Cu(110) surface in order to probe the chemistry associated with the build up of the metal film once the first copper layer has been grown [3]. A series of thermal stepwise conversions were identified, starting with the partial dissociative adsorption of the copper acetamidinate dimers into a mixture of monomers and dimers on the surface. On copper, an early dissociation of a C–N bond leads to the production of N-sec-butylacetamidine, which is detected in TPD experiments in three temperature regimes, the last one centered around 480 K. Butene, and a small amount of butane, is also detected above approximately 500 K, and hydrogen production, an indication of dehydrogenation of surface fragments, is observed at 460, 550 and 670 K. In total, only about 10% of the initial copper(I)-N,N'-di-sec-butylacetamidinate adsorbed monolayer decomposes, and only about ~3% of carbon is left behind on the surface

after heating to high temperatures. It is interesting to note that deposition of copper films with this precursor is dirtier on Cu(110) than on Ni(110).

Using the lessons learned from those initial studies, we have continued to tailor the structure of the precursors to minimize their side reactions. With the assistant of the research group of Sean Barry, a synthetic inorganic chemist, we have expanded our surface-science studies to Cu(I)iminopyrrolidinate and Cu(I)-guanidinate metalorganic compounds [4]. Specifically, the thermal chemistry of tetrakis[Cu(I)-N-sec-butyl-iminopyrrolidinate] and bis[Cu(I)-N,N-dimethyl-N',N"di-iso-propyl-guanidinate] was investigated on a Ni(110) single-crystal. Both precursors, which exist as tetramers and dimers in the solid phase, respectively, undergo dissociative adsorption at temperatures below 200 K to produce adsorbed monomers on the surface. A β -hydride elimination step is then operative near 300 K that leads to the release of some of the ligands in dehydrogenated form. The remaining adsorbates obtained from either precursor undergo similar further decomposition between 350 K and 600 K as the copper atoms are reduced from a Cu(I) oxidation state to metallic Cu(0). Hydrocarbons resulting from the elimination of the terminal moieties include ethene and acetonitrile from the Cu(I)-iminopyrrolidinate and propene from the Cu(I)-guanidinate, which are ejected around 420 - 490 K, and HCN in both cases at approximately 570 - 580 K. These results shows several similarities with the surface chemistry previously reported for bis[Cu(I)-N,N'-di-sec-butyl-acetamidinate], and suggest a common behavior in the surface reactions of these families of Cu(I)-amidinate, Cu(I)-iminopyrrolidinate, and Cu(I)-guanidinate ALD precursors. A schematic summary of these mechanisms is shown in Figure 1. This work has been extended to other surfaces (silicon oxide) [5] and to other types of precursors [6].



Figure 1. Mechanism for the thermal decomposition of the Cu(I) acetamidinate, iminopyrrolidinate, and guanidinate ALD precursors studied so far in this project. Highlighted are the weak bonds, those that are activated thermally to lead to the dissociation of the organic ligands and to the production of undesirable products. In the future, our goal is to stabilize the C–N bonds and to block the beta position to avoid β -hydride elimination steps.

Another area of research we have been pursuing is related to the deposition of manganese films as diffusion barriers in microelectronics. For this, the thermal chemistry of methylcyclopentadienyl manganese tricarbonyl (MeCpMn(CO)₃) on silicon oxide surfaces was characterized by a combination of analytical techniques, including gas chromatography-mass spectrometry (GC-MS) and infrared absorption spectroscopy in addition to TPD and XPS [7]. The compound was found to be fairly stable, but to be able to dissociatively chemisorb on the surface via the loss of one or more carbonyl ligands followed by the oxidative addition of a surface silanol group. Further activation leads to the loss of the aromatic ligand, at temperatures above approximately 575 K. GC-MS data indicates that this takes place primarily via the

addition of a hydrogen atom to the MeCp ligand to form methylcyclopentadiene, which is released to the gas phase, but a small competing channel starts at slightly lower temperatures that yields fulvene, and/or possibly benzene. after molecular rearrangement (Figure 2). The clean nature of the chemistry seen here for the methylcyclopentadienyl Mn complex makes it a good candidate as a precursor in the chemical deposition of metal thin films. However, the high stability and the high temperatures required for its decomposition do introduce some limitations.



Figure 2. GC-MS data indicating that the main decomposition pathway for $MeCpMn(CO)_3$ is a protonation step to produce methylcyclopentadiene. This makes the precursor promising for the deposition of clean films, but also difficult to activate.

Additional studies were carried out to test the further conversion of the Mn precursor on the surface using an oxidizing (N₂O) versus a reducing (H₂) co-reactant [8]. It was found that N₂O removes the majority of the MeCp adsorbed species, oxidizes the Mn silicide, and leads to the conversion of the MnO_x + SiO₂ oxide mixture into a Mn silicate top layer, whereas with H₂ only about half of the MeCp adsorbates can be removed in each cycle and only a small amount of additional Mn silicide is added in the second and third ALD cycles, but the original MnO_x + SiO₂ mixture is preserved and no significant increase in film thickness is detected.

Finally, a new process was developed to render surfaces selective toward ALD reactivity [9]. Specifically, a combination of silylation and UV/ozonolysis was tested as a way to control the concentration of the surface hydroxo groups required for subsequent atomic layer deposition (ALD) of metals or oxides. Water contact angle measurements were used to evaluate the hydrophilicity/hydrophobicity of the surface, a proxy for OH surface coverage, and to optimize the UV/ozonolysis treatment. Silylation with hexamethyldisilazane (HMDS), trichloro(octadecyl)silane (ODTS), or trimethylchlorosilane (TMCS) was found to be an efficient way to block the hydroxo sites and to passivate the underlying surface, and UV/O₃ treatments were shown to effectively remove the silylation layer and to regain the surface reactivity. Both

 O_3 and 185 nm UV radiation were determined necessary for the removal of the silvlation layer, and additional 254 nm radiation was found to enhance the process. ATR-infrared absorption spectroscopy was employed to assess the success of the silvlation and UV/O₃ removal steps, and AFM data provided evidence for the retention of the original smoothness of the surface. Selective growth of HfO₂ films via TDMAHf + H₂O ALD was seen only the UV/O₃ treated surfaces; total inhibition of the deposition was observed on the untreated silvlated surfaces (as determined by XPS and ellipsometry). Residual film growth was still detected on the latter if the ALD was carried out at high temperatures (250 °C), because the silvlation layer deteriorates under such harsh conditions and forms surface defects that act as nucleation sites for the growth of oxide grains (as identified by to electron microscopy, SEM). We believe that the silvlation-UV/O₃ procedure advanced here could be easily implemented for the patterning of surfaces in many microelectronic applications.

iii) Future Plans

In the next year, we plan to continue along the research directions already ongoing in this project. Specifically, we intend to extend our initial studies to:

- Design and test new copper acetamidinate precursors without beta hydrogens in order to minimize their side decomposition.
- Look into the surface chemistry of the recently reported copper ALD using a combination of hydrazine and formic acid as co-reactants. This project has already been initiated, but requires further work.
- Study the use of oxidation reactions as a way to reduce the metal precursors in ALD. This may sound counterintuitive, but is an approach that has already been successfully tested with late transition metals.
- Incorporation of reflection-absorption infrared absorption spectroscopy (RAIRS) to our tools of surface sensitive techniques.

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Utilizing Molecular Self-Assembly to Tailor Electrical Properties of Si Nanomembranes

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Program Scope

The program is focused on understanding the various interfacial phenomena, including self-assembly of organic molecules, charge injection, distribution, and separation at the organicinorganic hetero-interface that control electronic behavior. Interfacing organic molecules with semiconductors, in particular, with semiconducting nanostructures where materials transport properties are sensitive to surface and interface conditions offers a great opportunity to unravel the mechanistic basis of electronic interactions at hetero-interfaces. It can also potentially provide a nondestructive method for doping nanoscale semiconductors with molecular-scale precision. Technologically, the hetero-interfaces are crucial in the development of organic electronics, molecular electronics, molecular and biological sensors, and energy converting devices.

Recent Progress

Organic π -conjugated molecules have become emerging materials for applications including light-emitting diodes, field effect transistors, and solar cell devices, in the current electronics market.¹ In these device platforms, molecules are often deposited onto or placed in contact with inorganic surfaces. Thus the resultant device performances are highly correlated with the electronic structure, molecular orientation, and molecular ordering at the hetero-interface. This has stimulated intense interest in understanding and further tuning the interfacial electronic structure and the molecule-substrate interaction, particularly, searching for routes towards controlled well-ordered organic molecular growth.

Previously, we reported the discovery of an anisotropic crystalline organic step-flow growth on the deactivated Si surfaces. Access to the step-flow growth mode provides a means to achieve long-range in-plane molecular ordering. However, a deep understanding of the out-ofplane molecular ordering for growth beyond the first layer remains unexplored. Furthermore, there is still a lack of understanding of the underlying molecule-substrate binding mechanism and the origin of this long-ranged ordered growth at the molecular level. Also, to what extend the molecule-substrate coupling strength can be rationally tuned and how it impacts the potential landscape, which is critical for controlling the growth kinetics and the thin film morphology, need to be addressed.

Recently, we have explored the out-of-plane molecular ordering of multilayered zinc phthalocyanine (ZnPc) thin films on the deactivated Si(111)-B surface by scanning tunneling microscopy (STM) and low energy electron diffraction (LEED). A change in the in-plane crystallization corresponds to a change in the molecular configuration, which will likely result in a change in the interlayer spacing. As shown in Fig. 1 (a) and (b), LEED patterns at the coverage of 0.6 monolayers and 15 monolayers only display subtle differences as marked by the red hexagon and purple circle, suggesting only a minor variation in the in-plane molecular ordering with increasing coverage. This minor variation is associated with a slightly relaxed unit cell in the multilayered ZnPc films, as illustrated in Fig. 1 (d) and (e), but the azimuthal registration between the molecular layer and the substrate is maintained. LEED simulation (Fig. 1(c)) carried

out using the relaxed ZnPc unit cell agrees well with the experimental observation. In fact, depositing up to a coverage of 40 monolayers results in the same LEED pattern as observed in Fig. 1(b), indicating that a highly ordered molecular structure is maintained in multilayered ZnPc films. Since the molecules starting from the initial monolayer are tilted above the Si(111)-B surface by ~ 30° (see schematics in Fig. 2(b)), it offers a large π - π interaction between adjacent layers. We speculate that it is this strong interlayer molecular interaction that drives the high degree of out-of-plane ordering in the molecular thin films, which is able to be maintained without relaxing to the bulk-like structure despite the gradually decreased molecule-substrate interaction.

Fig. 2(a) shows a STM image of multilayered ZnPc film. Layer-by-layer growth is established within each Si terrace. However, a variation of layer thickness exists across the terraces due to the Ehrich-Schwöebel barrier associated with the Si step edges which prevents the downward mass transport of molecules. By decreasing the miscut of the Si substrate, the macroscopic roughness across the Si terraces will be reduced. This study contributes significant advances toward the formation of highly ordered molecular thin films both in-plane and out-of-plane which can be easily integrated into Si-based electronics or transferred to other substrates for organic device applications.



Next, we aim to establish a comprehensive understanding of the mechanisms of organic molecular growth on the deactivated Si(111)-B surface and the origin of this long-ranged ordered growth at the molecular level. Fig. 3 presents the surface topography of various MPc molecules deposited on the deactivated Si(111)-B surface with M=Zn, Cu, and Co respectively, where distinct molecular assembly and growth behaviors are identified. As shown in Fig. 3(a), ZnPc molecules adopt a tilted molecular configuration and crystallize to form densely packed structures. For CuPc, although it preserves the identical molecular orientation and packing motif as ZnPc, a notable degradation of the film quality is observed where a significant amount of gap defects and shifts in the molecular packing occur within the molecular domains (Fig. 3(b)).

Intriguingly, for the CoPc growth, we find that the molecules predominantly lie flat on the surface while the molecular patches with tilted configuration only emerge and are sparsely dispersed among the flat-lying molecules when the coverage is increased above a certain



Figure 3. STM images of (a) ZnPc, (b) CuPc, and (c) CoPc on Si(111)-B where ZnPc exhibits the highly ordered tilted molecular configuration, CuPc displays shifts in the molecular packing (dashed white lines) and gap defects (dashed red ovals), and CoPc shows both tilted and flat-lying molecular orientations. The green and blue bars represent individual Pc molecules with tilted configuration. (d-e) DFT calculated charge density difference maps shown for the molecular adsorption on the deactivated Si surface. Red regions denote electron accumulation while blue regions indicate electron depletion. The green balls represent top Si adatoms, and pink balls for subsurface borons.

threshold, as illustrated in Fig. 3(c).

This distinction is further corroborated by the difference observed in the initial molecular adsorption on the Si(111)-B surface. In contrast to CuPc where molecules display non-specific site registration with the deactivated Si surface, for the case of CoPc, both the Co ions and the 4 benzene rings preferentially register with the ad-Si atoms, as illustrated in Fig. 4(b) and (c). Due to the high degree of registration with the underlying surface, only 3 stable flat-lying CoPc orientations are allowed by the substrate symmetry, as highlighted by the red, blue and green rectangles. Such a drastically different molecular assembly and growth behavior observed for various MPc deposited on the Si(111)-B surface is in sharp contrast to the growth of these molecules on metallic surfaces where close-packed flat-lying molecular structures are formed regardless of the choice of the central transition-metal ion.²

Collaborating with Dr. Mina Yoon's group at ORNL, we have performed density functional theory calculations to account for the contrasting molecular adsorption and growth behavior of MPc on the deactivated Si(111)-B surface. By changing the metal ion from Zn to Co, the charge distribution within each orbital is altered and a depopulated d_{z2} orbital is formed in CoPc. The d_{z2} orbital, which is strongly localized on the central metal ion (over 90% of the molecular orbital), is the only symmetry-allowed orbital having nonzero overlap with the p_z state of ad-Si. Thus, a strong bond is anticipated to form between the singly-occupied d_{z2} orbital of CoPc and the Si adatom, leading to a significantly higher energy gain as compared to the case of ZnPc and CuPc. Figure 4(a) presents the key mechanism of selective orbital hybridization between the singly-occupied d_{z2} orbital of CoPc and the singly-occupied d_{z2} orbital of CoPc and the singly-occupied d_{z2} orbital of CoPc and the singly-occupied d_{z2} orbital orbital hybridization between the singly-occupied d_{z2} orbital of CoPc and the singly-occupied d_{z2} orbital orbital of CoPc and the singly-occupied d_{z2} orbital of CoPc and the empty p_z orbital of ad-Si. This hybridization effect is also manifested in the charge density difference plot upon the adsorption of MPc on the substrate. As presented in Fig. 3(d)-(f), the strong orbital hybridization introduces



Figure 4. (a) Schematic diagram of the orbital hybridization mechanism between a CoPc molecule and the Si(111)-B surface. (b, c) STM images of flat-lying CoPc on Si(111)-B, while the Co ion and the 4 benzene rings all register to the Si atatoms.

a significant charge accumulation on the p_z orbitals of ad-Si for CoPc (red regions in Fig. 3(f)), while a negligible or minute charge accumulation is observed for ZnPc and CuPc, respectively (Fig. 3(d) and (e)).

Thus far, we have identified a distinct mechanism of molecular binding to the substrate mediated by the central transition-metal ions. To further investigate the interplay between molecule-substrate interaction and molecular growth, the potential energy landscape of the surface is examined along selective directions where the internal molecular coordination (including rotation) is fully optimized at each point. For CuPc (similar trends are expected for ZnPc), along the two linearly independent diffusion pathways there are many local minima separated by low potential barriers that are mainly due to the vdW energy corrugation (Fig. 6(a)). Nevertheless, these small diffusion energy barriers can be easily overcome by intermolecular attraction, resulting in unhindered molecular diffusion of CuPc on the deactivated Si(111) surface. In contrast, in the case of CoPc, the potential energy landscape exhibits a deep potential well associated with a significant energy barrier that is over 1.2 eV (Fig. 6(b)). The small vdW potential energy corrugation (solid red line) indicates that this large energy barrier originates from the breaking of the chemical bond between the Co and the ad-Si atom as discussed previously. This chemical bond dominates the potential energy landscape and results in a strong localization of molecules on the surface.



Figure 5. (a) The energy landscapes of CuPc along the different diffusion pathways. Inset: Depicts the linearly independent minimum energy pathways for molecular diffusion. Circles denote the positions of Si adatoms. (b) The energy landscape of CoPc along the solid path as shown in inset in (a).

In summary, we have shown that the localized p_z orbitals on the Si(111)-B surface allow for highly selective orbital coupling with the *d*-orbitals of MPc molecules. By appropriately choosing the coordinated transition-metal ion in MPc to control the strength of the *p*-*d* orbital hybridization, the molecule-substrate interaction can be tuned accordingly. This leads to distinct molecular growth behavior ranging from a localized flat-lying molecular configuration to the formation of a highly ordered molecular thin film in a tilted configuration. The range of molecular ordering and orientation accessible with varying degree of molecular hybridization allows for the possibility of selecting a system exhibiting ideally balanced molecule-substrate and intermolecular interactions for forming well-ordered organic molecular growth that can be incorporated into modern electronics.

Future Plans

Beyond the topological control, it is also crucial to characterize electronic interactions at hetero-interfaces in order to utilize molecular adlayer as a nondestructive method for doping nanoscale semiconductors. To this end, we have utilized kelvin probe force microscopy to investigate interfacial charge transfer between various types of MPc molecules of differing electronegativity on ultrathin (15 nm) Si nanomembrane. We are currently concentrating on conducting transport measurements to evaluate the effects of surface chemical functionalization and interfacial charge transfer on electronic properties of Si nanomembranes.

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In Situ Visualization and Theoretical Modeling of Early-Stage Oxidation of Metals and Alloys

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Program Scope

Oxidation processes occurring at metal surfaces have tremendous importance in the environmental, chemical, energy, pharmaceutical, and microelectronics industries. A precise knowledge of the oxidation process and the atomic structure of the oxide layer is essential to improving existing processes and designing new functional materials. While several theories (e.g. Wagner-type diffusion theories, Cabrera-Mott model of electric-field driven oxide growth) have been formulated which explain and predict the oxidation behavior of many metals and alloys. they are satisfactory only over limited oxide thickness regions and often are not transferable to the initial stages of surface oxidation. The objective of this program is to bridge this information gap by developing an atomistic understanding of the microscopic processes governing the initial stages of oxidation ranging from oxygen surface chemisorption to the subsequent stages of oxide nucleation and growth. To this end, in situ microscopy and spectroscopy techniques are utilized to monitor, in real time and at the atomic and nanometer scales, the surface oxidation of a number of model systems of metals and alloys. Such in situ experimental data feed into the density-functional theory (DFT) modeling for identifying the critical kinetic and thermodynamic factors controlling the surface oxidation process including adsorption sites, diffusion path, reaction barrier, and surface/interface effects.

Recent Progress

A detailed understanding of the initial oxidation processes of surfaces has always been complicated by overwhelming inhomogeneities due to high density of defects. Atomic steps are present on virtually any crystalline material in any environment and serve as natural sources and sinks of substrate atoms owing to the reduced coordination of atoms at step sites. Through the use of a combination of *in situ* microscopy tools (low-energy electron microscopy (LEEM), aberration-corrected environmental transmission electron microscopy (TEM), and scanning tunneling microscopy (STM)) and theoretical modeling, we addressed oxidation induced surface dynamics as a result of mass transfer from and to steps. This is a critical issue since it influences both the mechanism and kinetics of many surface physical and chemical processes.

There has been intensive interest in understanding oxidation behaviors of NiAl alloys since NiAl is an attractive material for high-temperature applications for its a high melting point, low density, good oxidation and corrosion resistance. Understanding the initial oxidation of NiAl alloys is important to gain better insight into the oxide film growth and alloy degradation. Using LEEM that spatially and temporally resolves oxide film growth during the oxidation of NiAl(100), we demonstrated that surface steps are impermeable to oxide film growth. The advancement of the oxide occurs exclusively on the same terrace and requires the coordinated migration of surface steps. The resulting piling up of surface steps ahead of the oxide growth front progressively impedes the oxide growth [1]. This process is reversed during oxide decomposition. Fig. 1 exemplifies a sequence of *in situ* LEEM images of the oxidation of NiAl(100). The surface has a step-terrace morphology, where dark lines show the locations of atomic steps on the NiAl substrate and the center area has well separated steps. The oxidation

results in the growth of Al_2O_3 stripes with the supply of Al atoms from surface steps. A remarkable growth feature revealed from the *in situ* LEEM observation is that the oxide stripes

do not cross over substrate steps, instead, surface steps migrate in tandem with the advancement of the oxide stripes. Therefore, the oxide stripe pushes each substrate step that it encounters to advance jointly with the step edge in its path, which results in the bunching of a growing number of steps in front of the oxide stripe. These experiments demonstrated that an oxide stripe stays on the same terrace as it encounters either ascendant or descendant steps during the oxide growth or decomposition. By comparing with the oxidation of NiAl(110) that exhibits unimpeded oxide film growth over substrate steps [2-4], we suggest that whenever steps are the source of atoms used for oxide growth, they limit the oxidation process; when atoms are supplied from the bulk, the oxidation rate is not limited by



surface steps. The difference in the oxidation of NiAl(100) and (110) can be attributed to the effect of the crystallographic orientation. NiAl(110) has a less compact surface structure than NiAl(100), which may facilitate surface-bulk mass transport. For NiAl(100), the more compact surface structure makes surface steps kinetically more favorable as the source of Al atoms for oxide growth. This is further confirmed by our DFT calculations, which indicate that the energy barriers for the step-edge detachment on NiAl(100) are much smaller than those for NiAl(110).

Using *in situ* environmental TEM, we also visualized oxide film growth at atomic resolution during the oxidation of stepped Cu surfaces. We observed that the presence of surface steps leads to the decomposition of the oxide overlayer at the growth front, thereby resulting in oscillatory oxide film growth that proceeds in tandem with the propagation of the surface step. DFT calculations and *ab initio* molecular dynamics (AIMD) were employed to address the experimental observations. Fig. 2(a) shows *in situ* high-resolution



atoms for aluminum oxide growth.

Fig.2. (a) *In still* FIG1EM images of the growth of a single Cu_2O layer on a stepped Cu(110) surface at 350°C and $pO_2 = 5 \times 10^{-3}$ Torr; (b) Dependence of the growth length of the oxide film on time measured from the *in situ* TEM video, insets show schematically the different growth stages of the oxide film with respect to the propagation of the surface step of the Cu substrate.

TEM images of the oxidation of a Cu(110) surface. The oxidation proceeds through the growth of a single Cu oxide layer on the Cu(110) surface. The Cu surface consists of two wide terraces separated by a \sim 5-Å height step-bunched region. The *in situ* TEM observation shows that the oxide layer does not sweep across the stepped region unimpeded. Instead, the stepped region moves synchronously with the oxide growth. Such in-step propagation is interrupted when the substrate step flow does not keep up with the oxide growth, and the growth front of the oxide layer reaches the downward edge of the Cu terrace. The oxide layer is seen to retract from the

terrace edge and then resumes its growth. Once the oxide growth front catches up with the step edge again, it undergoes another cycle of retraction/re-growth. Fig. 2(b) shows the evolution in the length of the oxide layer measured from the *in situ* TEM video. Insets in Fig. 2 show schematically several key stages of the observed oscillation (TEM electron-beam irradiation has a negligible effect on the observed oscillation as evidenced by the lack of oscillatory growth on flattened surface under the imaging condition). Our *in situ* TEM observations also demonstrated that the oscillatory oxide growth is not tied to a particular step-edge configuration [7], implying the broader applicability of the results to other systems. Indeed, similar oscillation in the growth of Al_2O_3 films in step-bunched regions was also observed from our *in situ* LEEM observations of the oxidation of NiAl(100).

Using in situ STM, we provided direct evidence that surface steps are the source of Cu adatoms for the Cu(110)-(2×1)-O restructuring [8]. As shown in Fig. 3, a screw dislocation intersects the Cu(110)surface, which results in the presence of a monoatomic-height surface. With increasing O coverage, -Cu-O- rows form stripe-shaped domains of the (2×1) -O reconstruction with coordinated retraction of the surface step from its original position, which demonstrates rather nicely that Cu atoms are



Fig. 3: Consecutive topographic STM images of the Cu(110) surface showing the retraction of a surface step upon the nucleation and growth of -Cu-O- added rows with oxygen exposure at $pO_2 = 1 \times 10^{-10}$ Torr and T = 25 °C. Bottom left insets: DFT calculations of Cu-O dimer formation with Cu step-edge detachment; Top right insets: Snapshots of KMC simulations with the reaction paths and energy barriers identified from the DFT calculations.

removed from the step edge to supply the growth of -Cu-O- added rows. Using STM, we also demonstrated that the Cu(110) surface restructuring proceeds via a sequential pathway of $(2\times1) \rightarrow c(6\times2)$ through a mechanism that consumes the existing (2×1) phase and depletes the underlying Cu terrace atoms. We employed DFT, AIMD, and NEB techniques to study the $(2\times1) \rightarrow c(6\times2)$ transition. We found that the transition from a configuration containing four Cu-O-Cu-O chains to the $c(6\times2)$ structure requires the concerted movement of three Cu atoms with an associated energy barrier of 1.41 eV [9], which is suggested as the origin of the kinetic hindrance that causes discrepancy between experimental observations and the theoretical O/Cu(110) equilibrium phase diagram obtained by the first-principle thermodynamics [10].

Future Plans

Sub-surface O incorporation represents a crucial step for initiating oxide formation. Developing a deep understanding of O penetration below metal and alloy surfaces is of importance not only for controlling the initial stages of metal and alloy oxidation but also for harnessing many other technologically important processes involving sub-surface O penetration, such as catalysis, oxygen storage at a metal/oxide interface, and metal passivation. We will elucidate the energetics and kinetics of O sub-surface adsorption and determine how they depend on the surface structure, morphology and composition with the research goal of controlling sub-surface oxidation via tuning O sub-surface incorporation. Two different experimental systems, i.e., surface orientation and surface alloying, along with the effect of temperature and oxygen pressure, will be investigated for establishing the principles capable of predicting the trend and controlling the process of sub-surface O adsorption. We will also study the atomic process governing the transformation of the crystal lattice of the parent metal into its oxide upon further subsurface O adsorption. Gaining a deeper knowledge of the oxide formation pathway is

essential not only for understanding the oxidation mechanism but has also practical importance because the likely lively dynamics between the metastable and stable configurations will affect the surface chemical properties under realistic conditions, and, for instance, any catalytic reactions taking place over them.

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Growth And Properties Of New Epitaxial Metal/Semiconductor Nanocomposites

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Program Scope

Nanocomposites consisting of nanoparticles (such as ErAs) within III-V semiconductors represent a useful alternative to conventional materials for a variety of applications. The incorporation of nanoparticles into semiconductors can pin the Fermi level, drastically altering the electronic properties in ways that are fundamentally different from conventional doping. Carrier concentrations and dynamics can be altered, and phonon scattering of medium wavelength phonons can be observed. These effects allow applications such as terahertz source and detectors, thermoelectrics, enhanced tunnel junctions for multijunction solar cells, and others. These materials have been studied using molecular beam epitaxy (MBE)-grown materials, and the epitaxial relationship between the rocksalt crystal structure of the nanoparticles and the zincblende structure of the matrix allows high quality interfaces, allowing the study of the fundamental charge transfer mechanisms in nanostructured electronic composites.

Although the prior work by MBE has enabled significant advances in the understanding of a subset of this class of composite materials, the hallmarks of MBE-grown material are a lack of flexibility in composition, a slow growth rate, and very high cost. To these ends, this project is focused on creating epitaxial nanocomposites via a hybrid approach in which nanoparticles are produced using inert gas condensation (IGC) and incorporated epitaxially into semiconductor films using liquid phase epitaxy (LPE). This approach allows a wider crosssection of these materials to be studied by providing independent control over nanoparticle production and film growth. Additionally, from a technological point of view, the hybrid approach should allow growth rates of micrometers per minute rather than micrometers per hour, thus allowing thicker films and scaling of materials. The fundamental goal of this program is to develop this new growth approach and apply it to the study of this class of materials. Because this is a fundamentally new approach to nanocomposite synthesis, it presents many new challenges and also many new opportunities. As described below, many obstacles have been addressed, but as we overcome these obstacles, we can expand this approach beyond this particular class of materials in the hopes of establishing a new paradigm in nanocomposite synthesis for electronic materials.

Recent Progress

IGC Growth of ErAs

Because this program centers is based on a fundamentally new synthesis approach, we have encountered many challenges over the past two years. The first requirement of the program was the ability to generate controlled ErAs nanoparticles via inert gas condensation (IGC). Several changes have been made to the initial design of the IGC approach for this material system to improve performance. Due to relatively high operating pressure (5-100 torr of He gas), the arsenic source was changed from a valved arsenic cracker to the simultaneous ablation of both erbium and arsenic by a pulsed Nd:YAG laser. This allows for a more spatially confined

interaction region for the two vapors, leading to higher purity nanoparticles. Source powders are compressed into pellets, which are then placed into glass beakers; the walls of which serve as the collection substrate. The large collection area allows for hundreds of milligrams of powder to be collected at a time, resulting in a much higher yield than typical magnetron sputtering techniques for nanoparticles. Particles that are collected on the beaker are then scraped into a vial using a stainless steel scraper inside a glove bag attached to the chamber.

Through systematic experimentation, we have determined conditions appropriate for creating ErAs nanoparticles with sizes of 5 ± 1 nm diameters. This is the first demonstration of the growth of ErAs nanoparticles without a host matrix. A transmission electron microscopic (TEM) image of the ErAs particles is shown in Figure 1 along with the selected area electron diffraction (SAED) pattern obtained from the area. Powder x-ray diffraction (PXRD) and energy dispersive spectroscopy (EDS) are used to confirm the presence of ErAs as well as characterize

other compounds in the resultant nanoparticle powders. From XRD analysis, we are able to confirm that the powders contain as much as 76% ErAs. Other phases present in the powders include (as expected) erbium, erbium oxide, arsenic, and arsenic These byproducts do not oxide. represent a problem; erbium itself acts as a gettering agent in the LPE growth of GaAs films, improving the overall film quality, and arsenic is already added to the LPE melt before it can be used for growth.



Figure 1: (a) TEM image (with corresponding SAED pattern, inset) for ErAs nanoparticles grown by IGC, (b) particle size distribution

Discovery and Characterization of new Er-As Phase

One of the opportunities presented by a new synthesis approach is the possibility of unexpected discoveries. Previously, only one phase of ErAs (specifically, the rocksalt monopnictide) was known to exist. While theoretical predictions of other phases have been made recently [1], we were excited to discover a phase that does not exist on any phase diagrams.



Figure 2: (a) XRD pattern of new phase observed (b) TEM image of particles and corresponding SAED pattern. Lattice fringes show crystalline nanoparticles.

Produced under erbium-rich growth conditions, this phase appears (from PXRD) to have a cubic $Pm\overline{3}m$ [221] structure with a lattice constant of approximately $a = 4.08 \text{ Å} \pm$ 0.01Å. EDS and SAED patterns obtained from TEM analysis of this sample agree with the XRD results and suggest that the compound is Er-rich. (Figure 2) We have begun collaborations with Dr. James LeBeau and Dr.

Anderson Janotti to determine the crystal structure of this compound using scanning transmission electron microscopy (STEM) and density functional theory (DFT), respectively, to more accurately identify this phase and any important properties which it may possess.

LPE Growth of GaAs and ErAs:GaAs

The first objective of the work on thin film growth by liquid phase epitaxy (LPE) was to demonstrate the uniform growth of GaAs on a GaAs substrate. As growth conditions described in literature vary widely, optimization of these seemingly-simple growth conditions led to some initial delays. At the same time, proper control over growth conditions is a prerequisite for high-quality growth of nanocomposites. Recently, we have attempted to incorporate nanoparticles into the thin film by adding these nanoparticles obtained from IGC into the melt for LPE growth. The thin films that were grown with these melts were first characterized with spectrophotometry and

Transform Infrared Fourier (FTIR) spectroscopy. as these are rapid characterization tools commonly used to study films grown with MBE. [2] While absorption features were observed in these first samples, the absorption intensity is reduced compared to MBE grown films. TEM study does appear to show the incorporation of particles (Figure 3), but quantification has not been possible. We attributed these observations to a relatively low concentration of ErAs nanoparticles in the melt, and have since increased the concentration from $\sim 0.1\%$ to $\sim 5\%$. This change in the melt composition has changed the growth window somewhat for GaAs thin films, and we are now working to optimize growth conditions control the incorporation to of nanoparticles into the films.



Fig. 3: TEM micrograph of ErAs:GaAs film. Inset: SAED of this region; the apparent polycrystallinity of the inclusion phase is not yet understood.

Future Plans

IGC Growth of Nanoparticles

We are currently working on controlling the size of particles that we are able to produce via the IGC method. Ideally, we would like to have particles that are ~1-2 nm in diameter in order to directly compare to MBE grown films. However, wider particle size distributions is actually beneficial for thermoelectric materials, as different size particles are able to scatter phonons of different wavelengths. Most fundamentally, control of particle size, while elusive in MBE, gives the ability to study surface vs. volume effects in nanoparticle-containing systems.

Other avenues of research in the near future include investigating the recently-discovered new phase further to try to identify any useful properties it may contain and the growth of other rare-earth arsenides, (namely Tb and Nd), which will begin in the next few months. Another topic of interest that merits further investigation is the oxidation of ErAs nanoparticles. Previous
work on ErAs thin films has shown that they oxidize rapidly, requiring a capping layer in order to be studied[3]. Initially, the IGC chamber was designed so that particles could be incorporated into a Ga melt without any exposure to air. However, it appears that the particles are able to remain stable in air or ethanol for moderate amounts of time (weeks). We are currently collaborating with Dr. Robert Opila to complete x-ray photoelectron spectroscopic analysis of the oxidation of these particles. An understanding of the oxidation of these particles allows the study of electronic band structure, which is a critical complement to existing studies performed in embedded-nanoparticles.

LPE Growth of Nanocomposites

As we complete our systematic study of the effects of growth conditions on film morphology and nanoparticle incorporation, we hope to expand our study of film morphology using STEM. As this growth approach becomes mature, we plan to study thermal and electrical properties of these materials. More specifically, Hall effect will be used to measure carrier concentration and mobility, while Seebeck measurements and thermal conductivity measurements (using time-domain thermoreflectance) will be employed to study thermoelectric properties. Through a long-standing collaboration with researchers at Los Alamos National Laboratory (through the CINT program), we intend to study the carrier dynamics in these materials. More importantly, as new nanoparticles are produced, we can uses the ErAs:GaAs results as a benchmark for the study of this otherwise-underexplored class of materials.

Additionally, the LPE growth of InGaAs thin films on InP is an established technology [4], and we intend to study nanocomposites with this alternate matrix material for applications in thermoelectrics and terahertz devices.

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